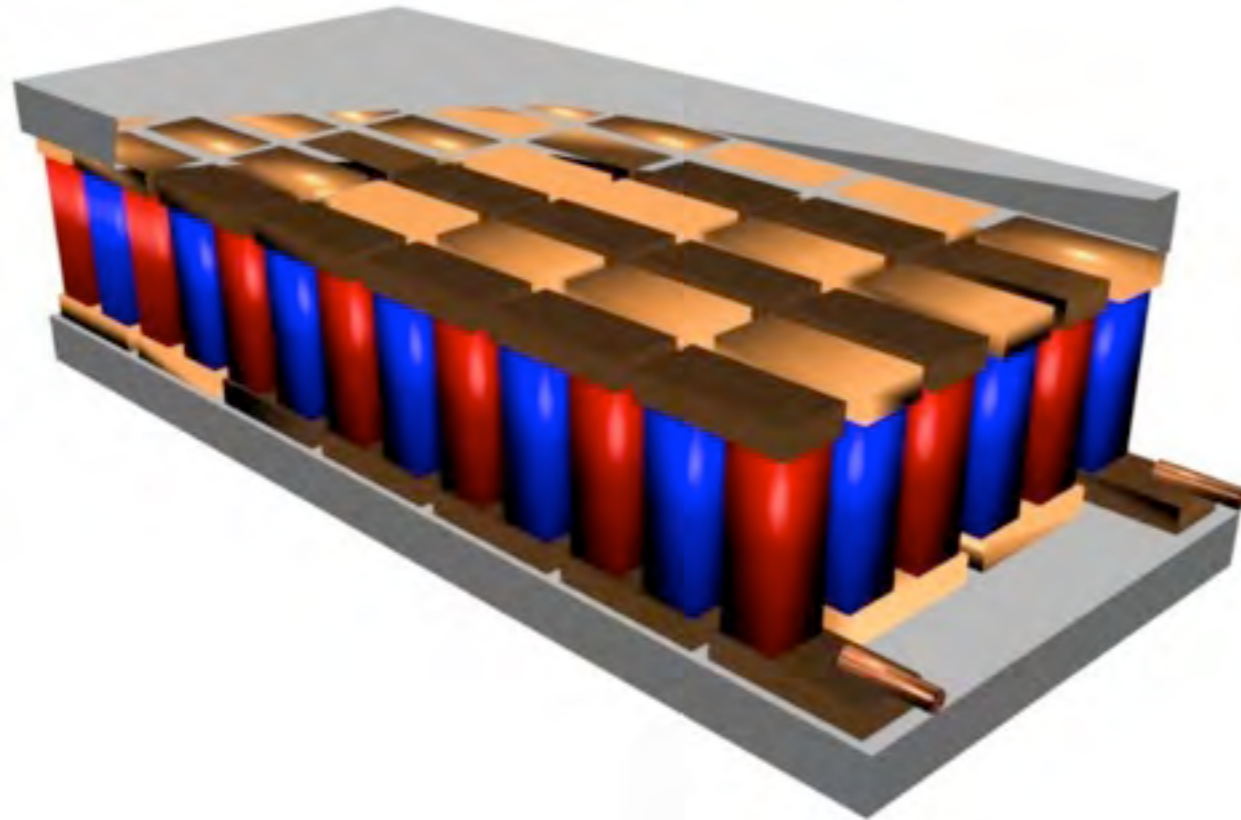


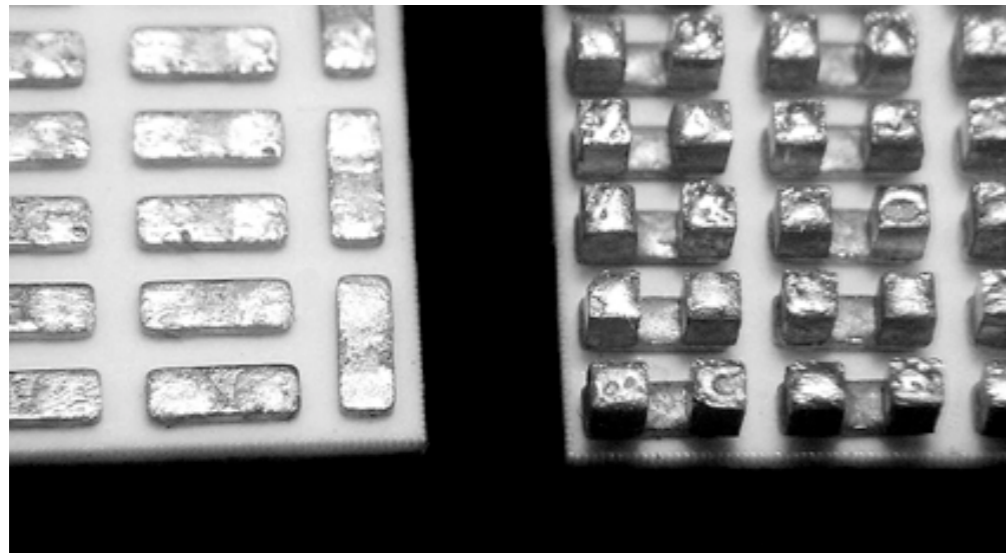
# Thermoelectric Energy Harvesting



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***D.J. Paul***  
***School of Engineering***



**University  
of Glasgow**

- **Established in 1451**
- **7 Nobel Laureates**
- **16,500 undergraduates, 5,000 graduates and 5,000 adult students**
- **£130M research income pa**



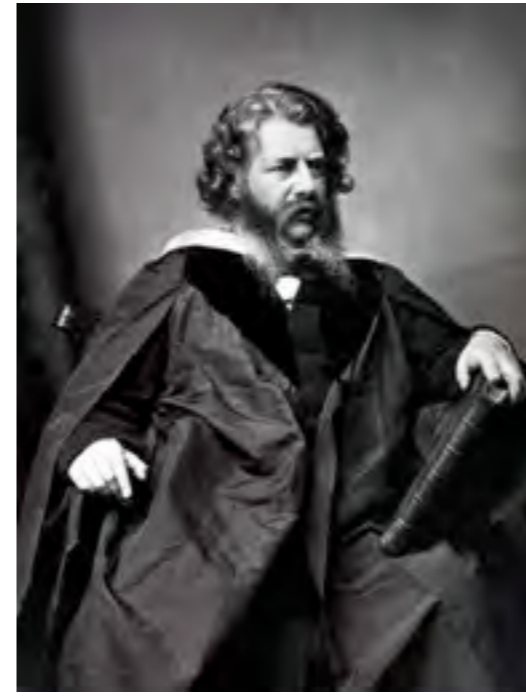
- **400 years in High Street**
- **Moved to Gilmorehill  
in 1870**
- **Neo-gothic buildings by  
Gilbert Scott**



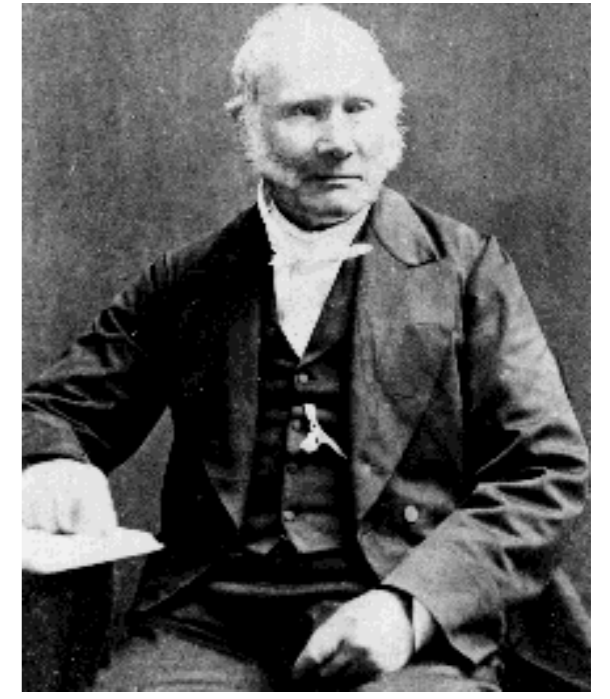
**William Thomson  
(Lord Kelvin)**



**James Watt**



**William John  
Macquorn Rankine**



**Rev Robert Stirling**



**Rev John Kerr**



**Joseph Black**



**John Logie Baird**



**Adam Smith**

## Vistec VB6 & EBPG5



E-beam lithography



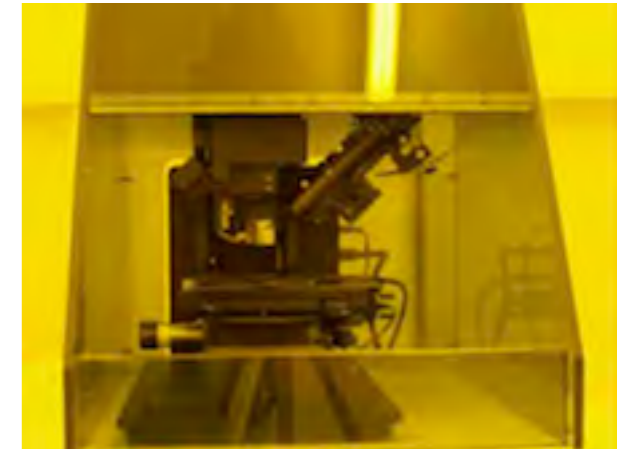
Süss MA6 optical lith

## 10 RIE / PECVD



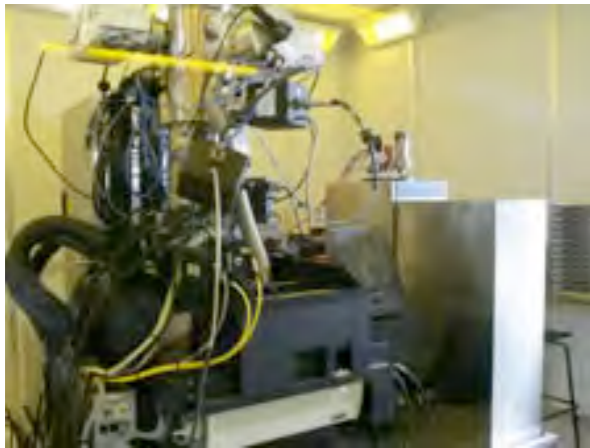
- 750 m<sup>2</sup> cleanroom - pseudo-industrial operation
- 18 technicians + 4 PhD technologists
- EPSRC III-V National Facility
- Processes include: MMICs, III-V, Si/SiGe/Ge, integrated photonics, metamaterials, MEMS (microfluidics)
- Commercial access through Kelvin NanoTechnology
- <http://www.jwnc.gla.ac.uk>

## 5 Metal dep tools    4 SEMs: Hitachi S4700    Veeco: AFMs



**30 years experience of e-beam lithography**

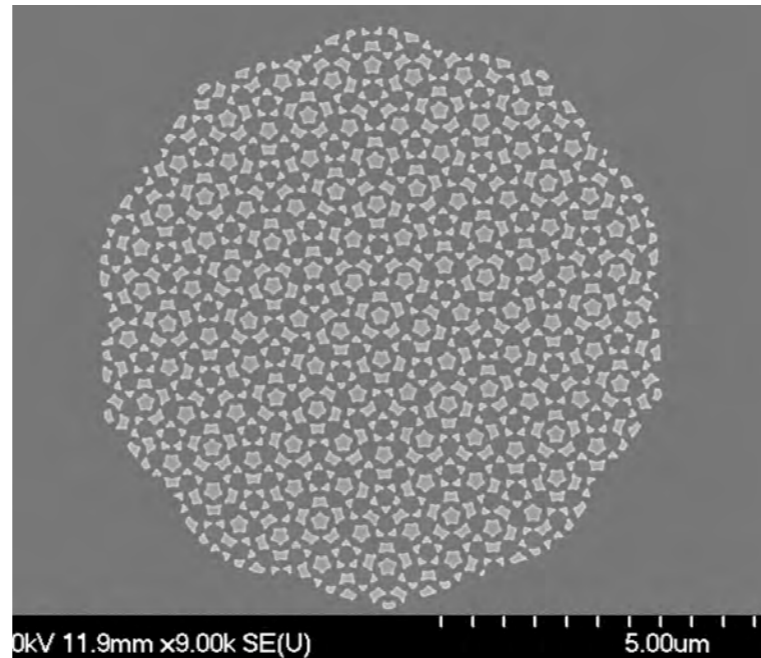
**Sub-5 nm single-line lithography for research**



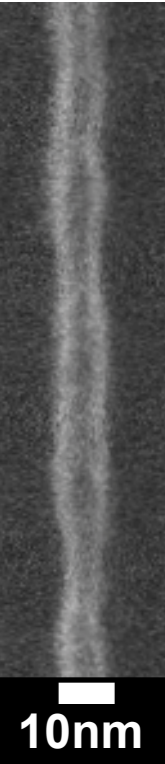
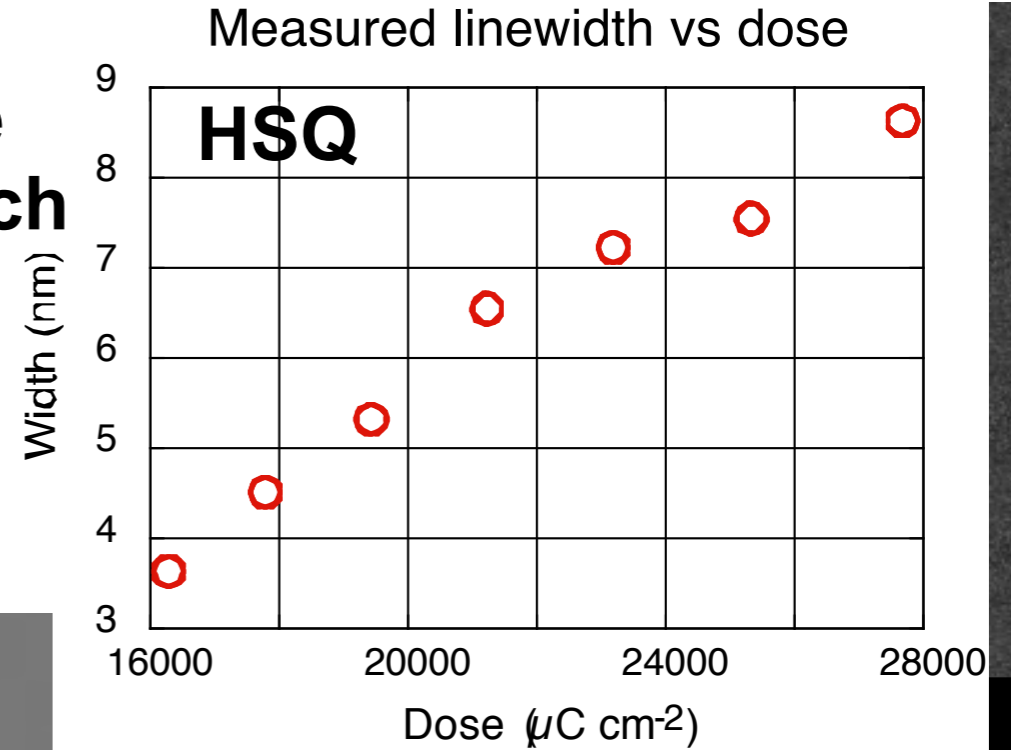
**Vistec VB6**



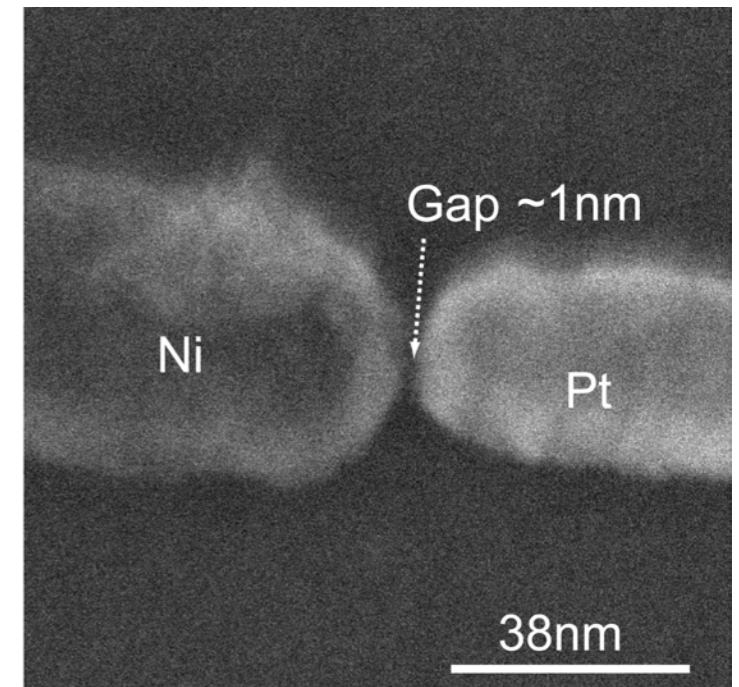
**Vistec EBPG5**



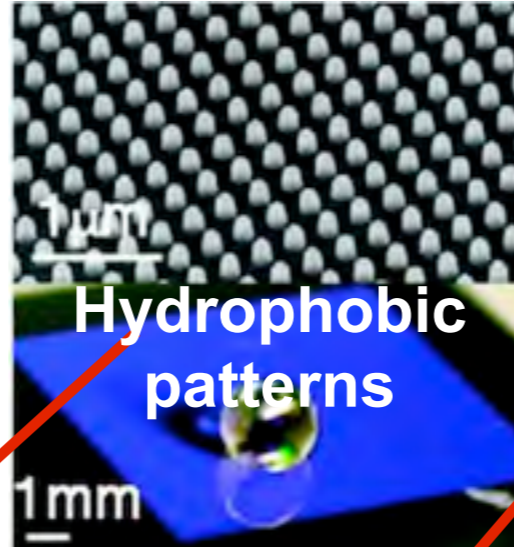
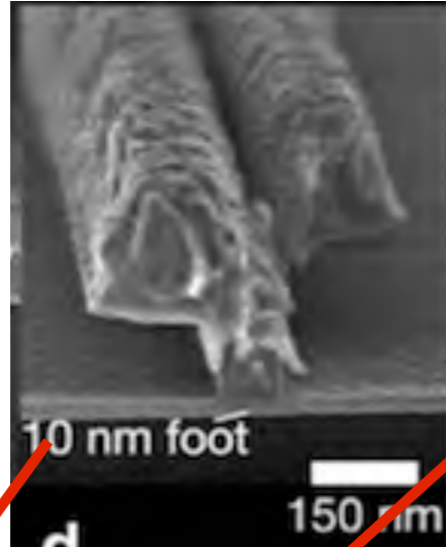
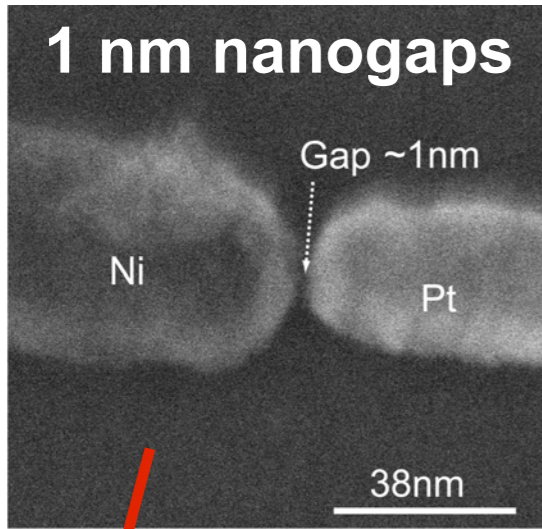
**Alignment allows 1 nm gaps between different layers**



**Penrose tile: layer-to-layer alignment 0.46 nm rms**



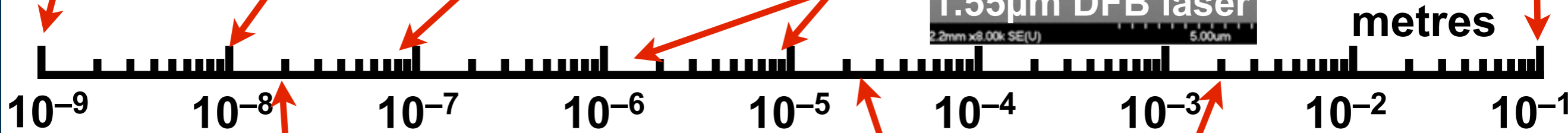
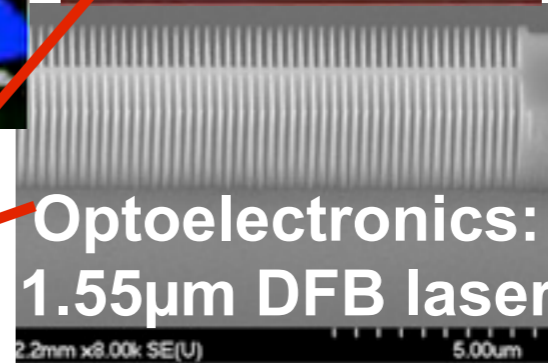
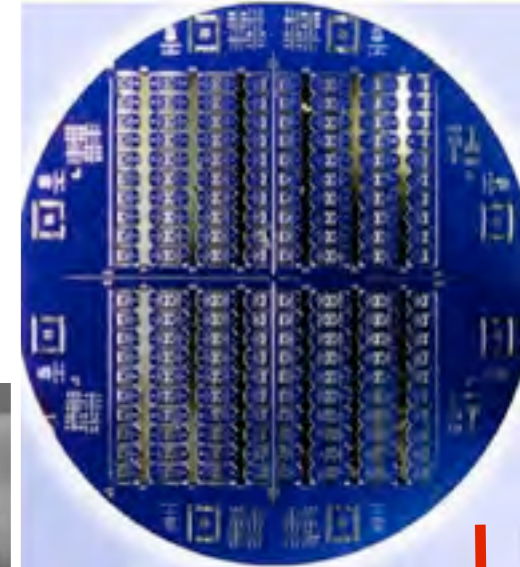
## Nanoelectronics: 10 nm T-gate HEMT



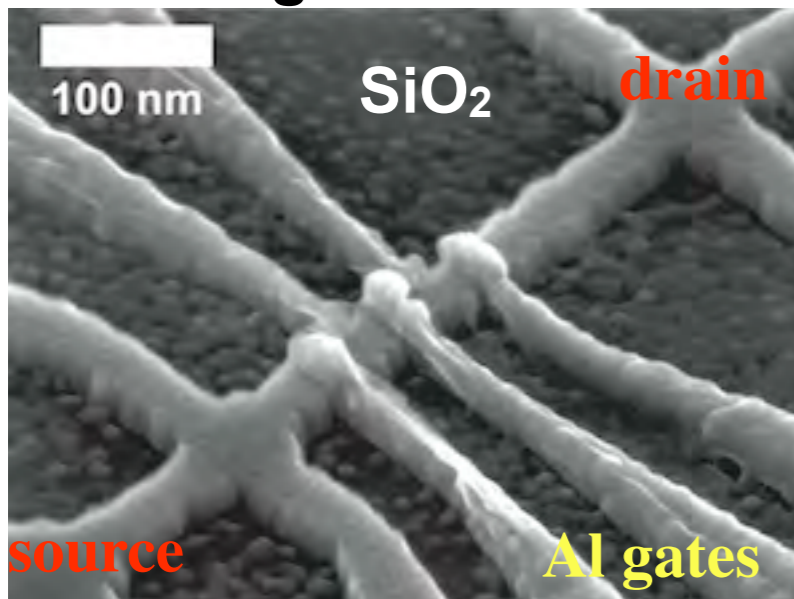
## Healthcare: STEM cell interrogation



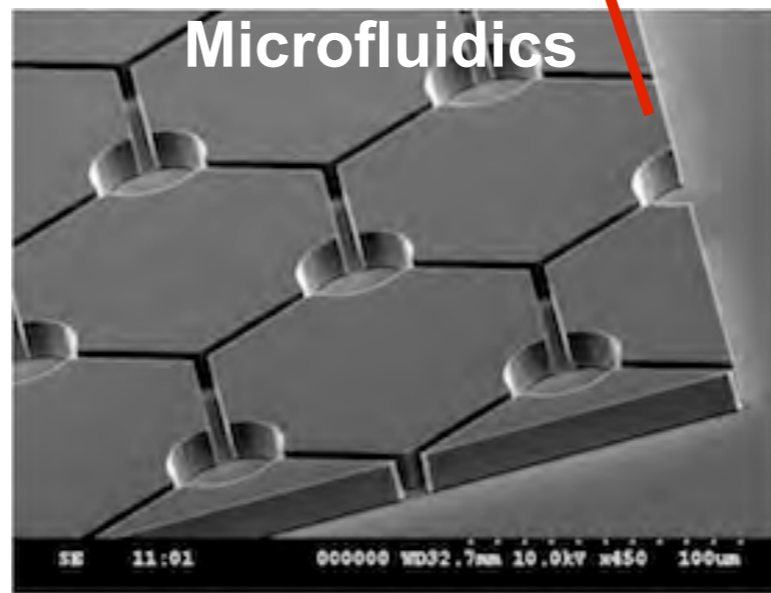
## Manufacture: AFM probes



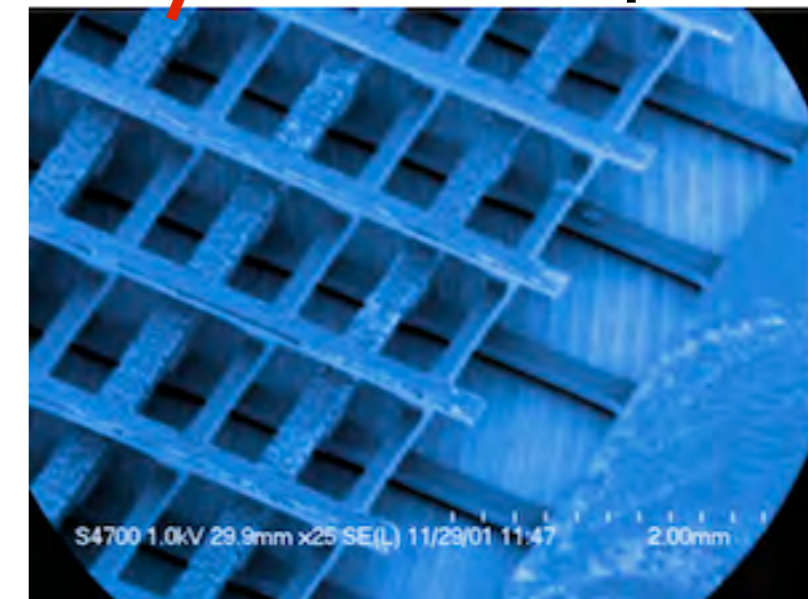
## Sensing: Si nanowires

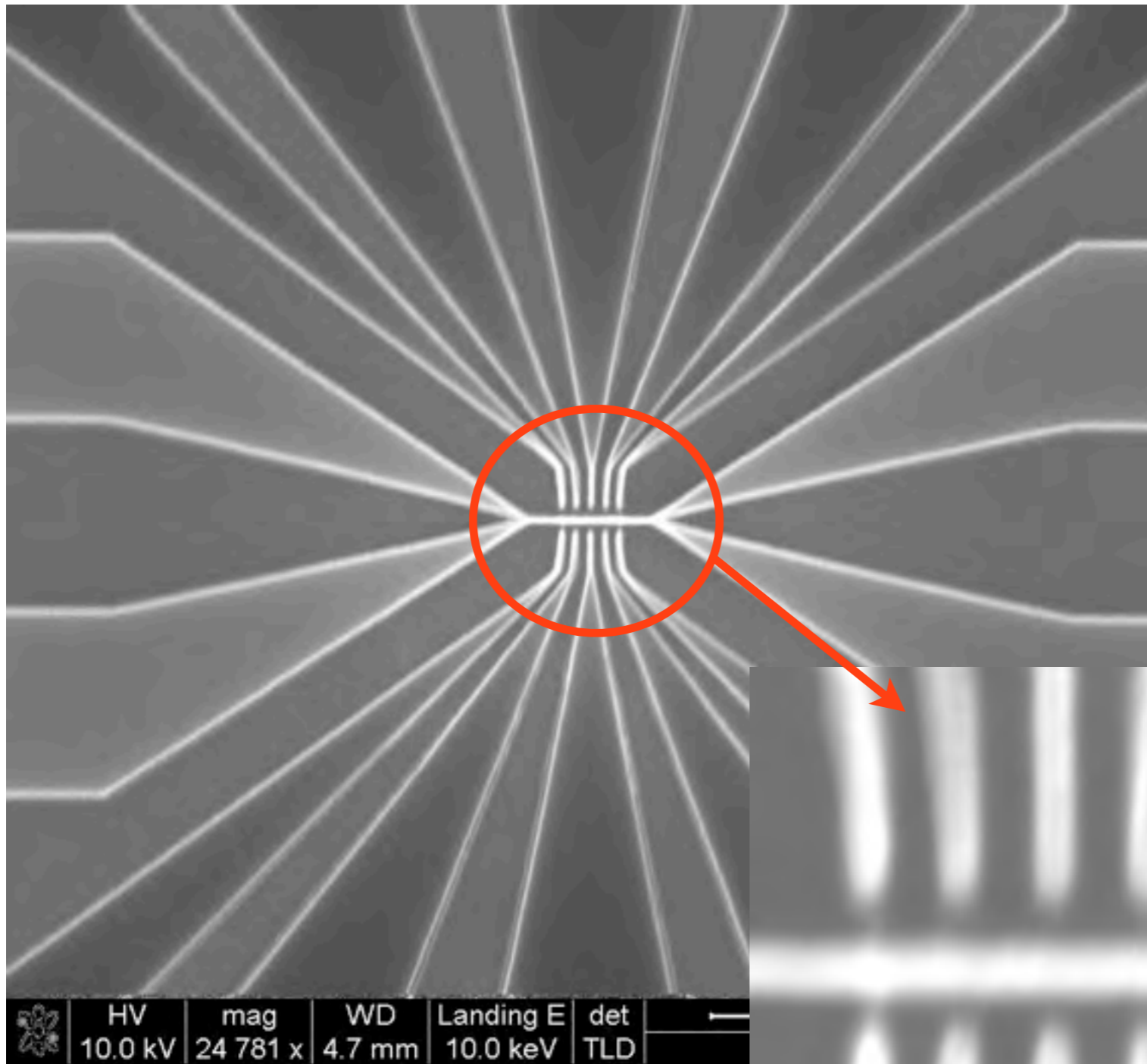


## Environment: Microfluidics



## MEMS: THz optics

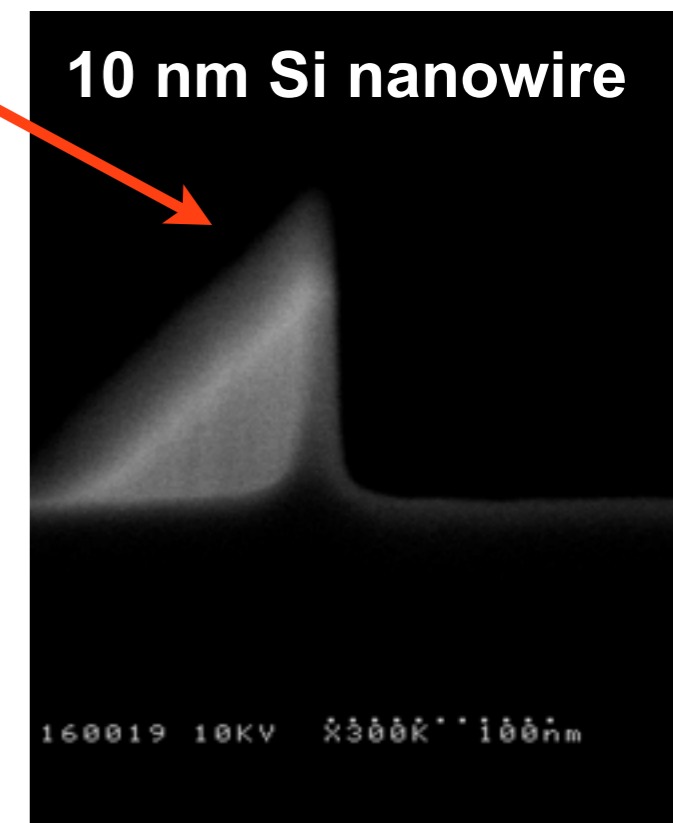
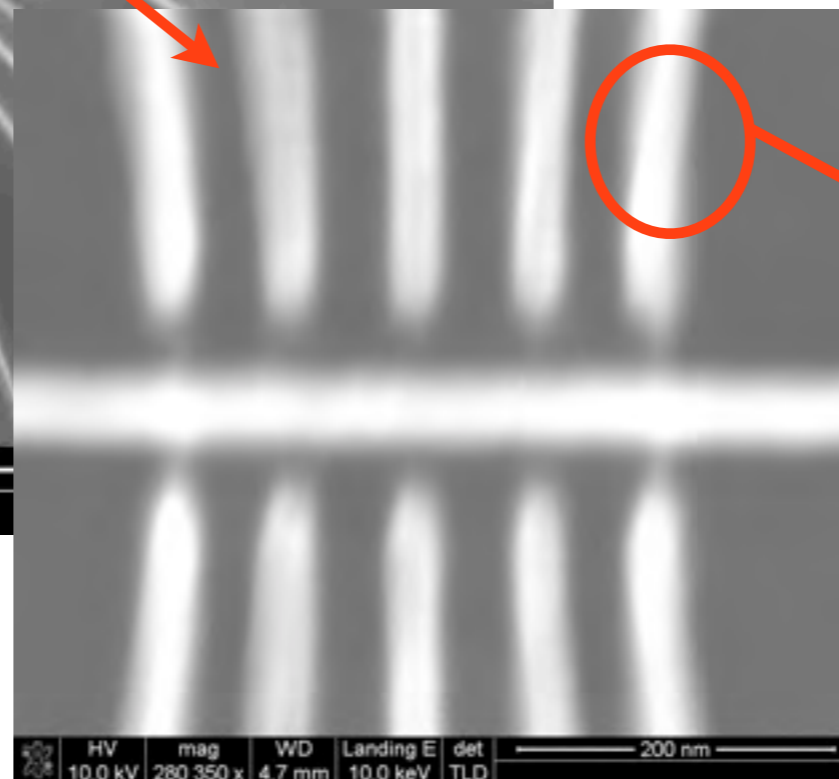




**10 nm features achieved for SET devices**

**Electrical properties now being optimised**

**Example of low damage process integration**



**10 nm wires with 10 nm spacing**

# Thermoelectrics History

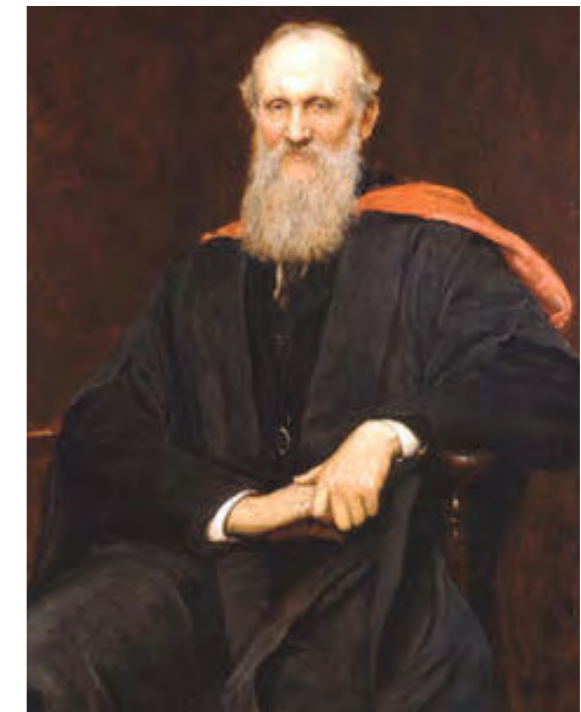
- History: Seebeck effect 1822



heat → electric current



- Peltier (1834): current → cooling



- Thomson effect: Thomson (Lord Kelvin) 1850s



# Thermoelectric History and Early Applications

- Ioffe: physics (1950s), first devices 1950s - 1960s, commercial modules 1960s

## Early applications:

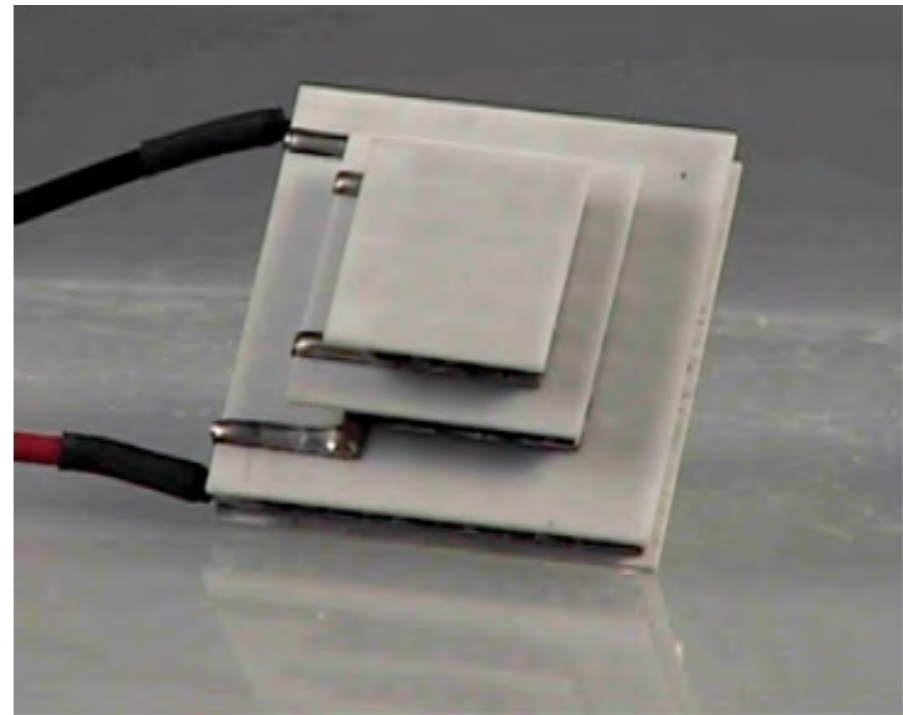
- Peltier coolers for military applications - rf / mm-wave electronics
- Peltier coolers for civilian applications (telecoms lasers, beer! etc...)
- Thermoelectric generators for deep space missions (NASA)
- Thermoelectric generators – industrial energy harvesting (oil drilling)

**As renewable energy interest increases, renewed interest in thermoelectrics**

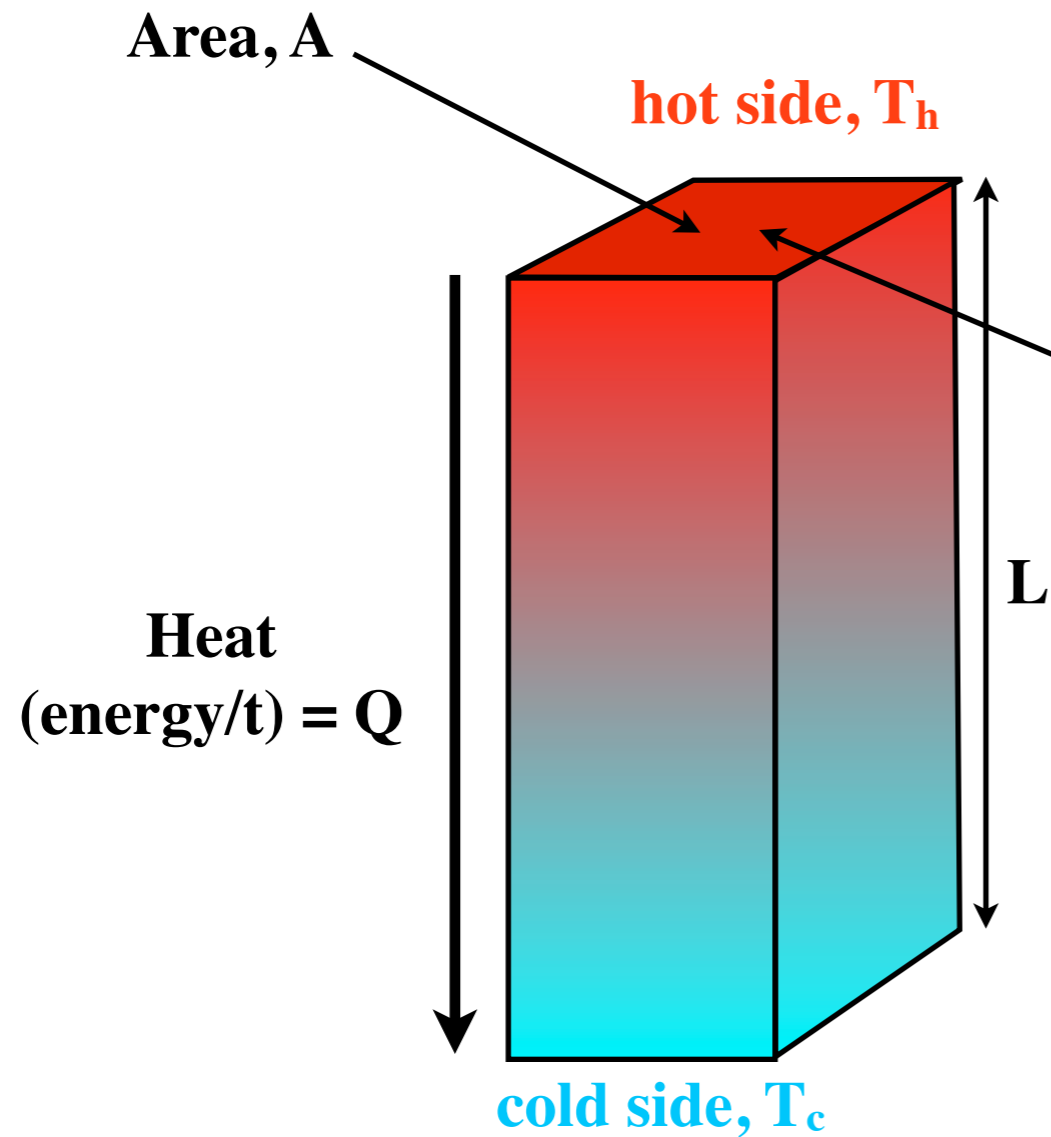
# Why Use Thermoelectrics?

- No moving parts → no maintenance
- Peltier Coolers: fast feedback control mechanisms →  $\Delta T < 0.1 \text{ }^\circ\text{C}$
- Scalable to the nanoscale → physics still works (some enhancements) but **power**  $\propto$  **area / volume**
- Most losses result in heat
- Most heat sources are “static”
- Waste heat from many systems could be harvested

**home, industry, background**



# Fourier's Law of Heat Conduction

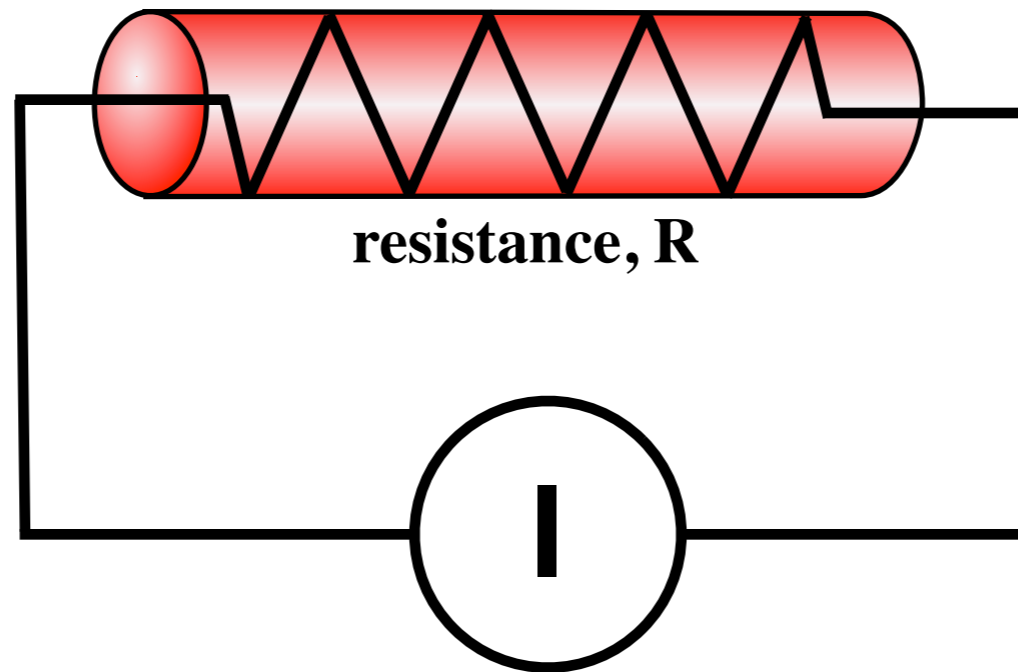


$$Q = -\kappa A \frac{T_h - T_c}{L}$$

negative since heat is removed from this end and conduction reduces thermoelectric effects

$$Q = -\kappa A \nabla T$$

# Joule Heating



$$Q = I^2 R$$

$Q = \text{heat} = \text{power} = \text{energy} / \text{time}$

# Background Physics

## Fourier thermal transport

$$Q = -\kappa A \nabla T$$

**Q** = heat (power i.e energy / time)

**E<sub>F</sub>** = chemical potential

**V** = voltage

**A** = area

**q** = electron charge

**g(E)** = density of states

**k<sub>B</sub>** = Boltzmann's constant

## Joule heating

$$Q = I^2 R$$

**R** = resistance

**I** = current (**J** = I/A)

**κ** = thermal conductivity

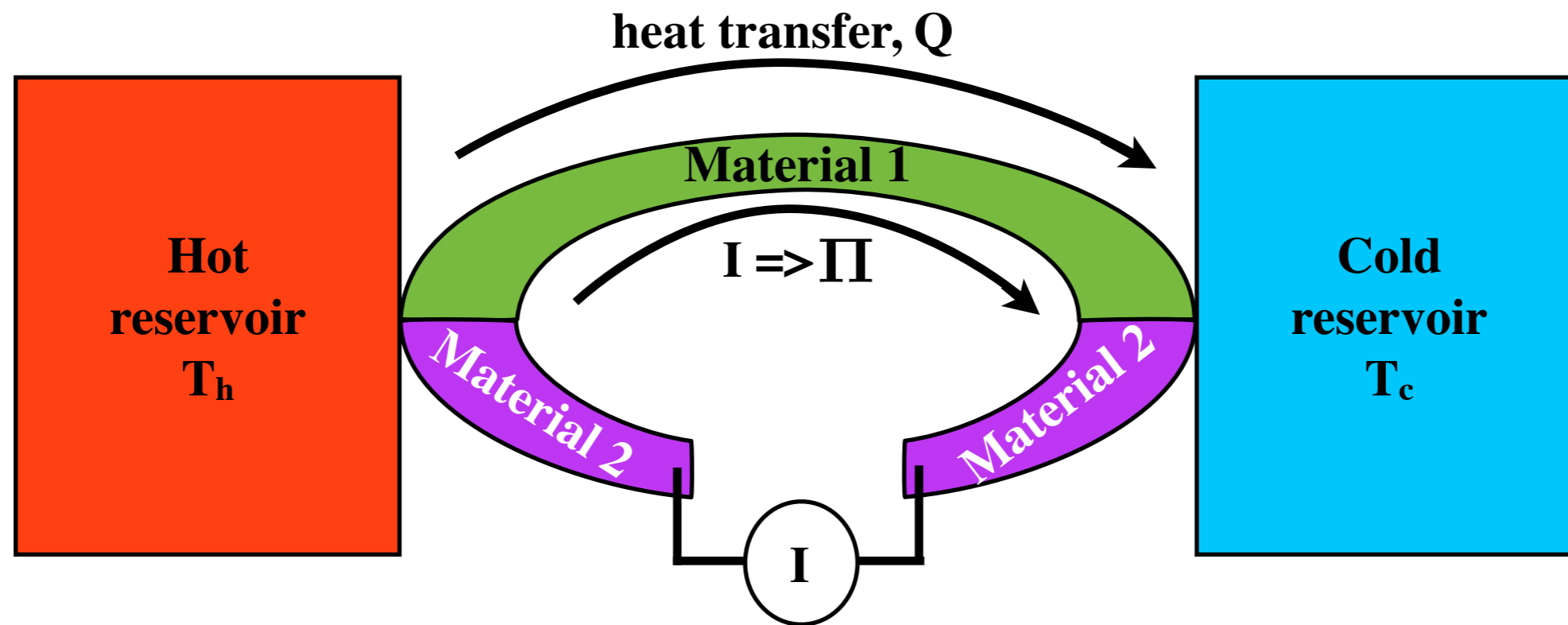
**σ** = electrical conductivity

**α** = Seebeck coefficient

**f(E)** = Fermi function

**μ(E)** = mobility

# The Peltier Effect



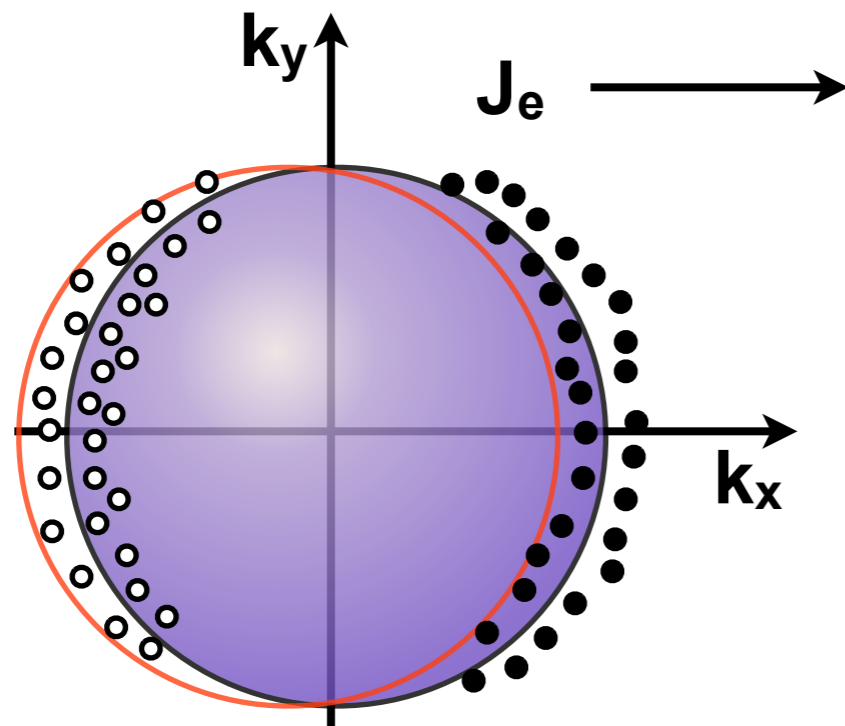
Peltier coefficient,  $\Pi = \frac{Q}{I}$

units:  $W/A = V$

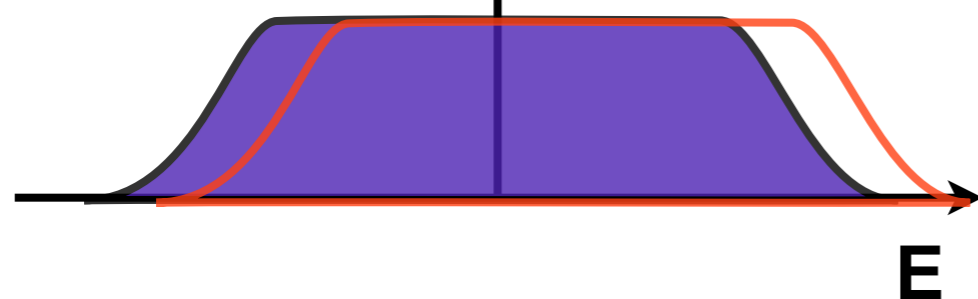
- Peltier coefficient is the energy carried by each electron per unit charge & time

# 3D Electronic and Thermal Transport

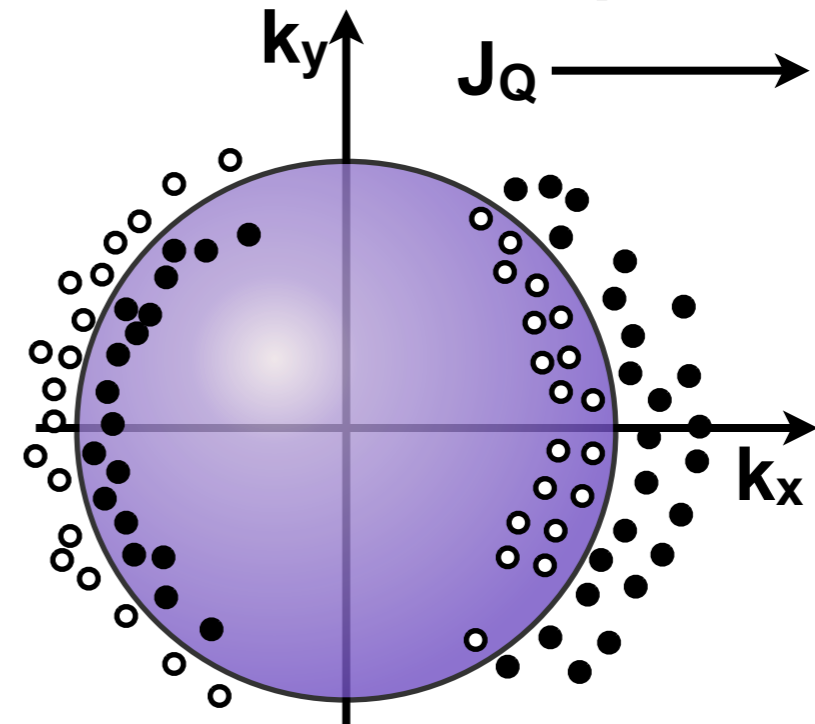
## 3D electronic transport



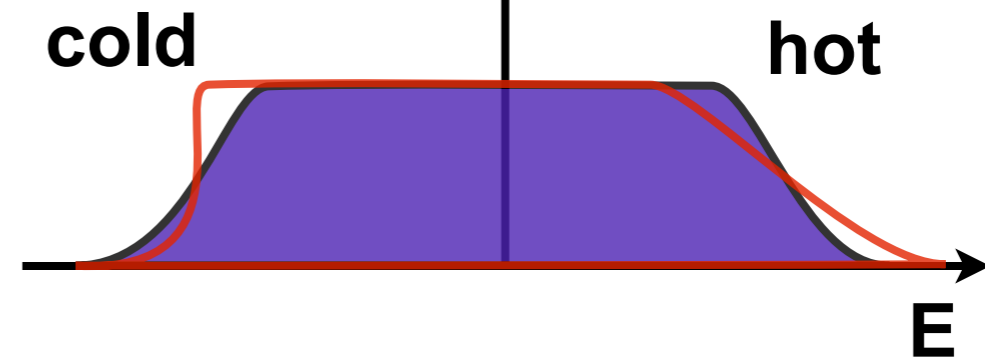
$$f(E) = \frac{1}{\left[1 + \exp\left(\frac{E - E_F}{k_B T}\right)\right]}$$



## 3D thermal transport



$$f(E)$$



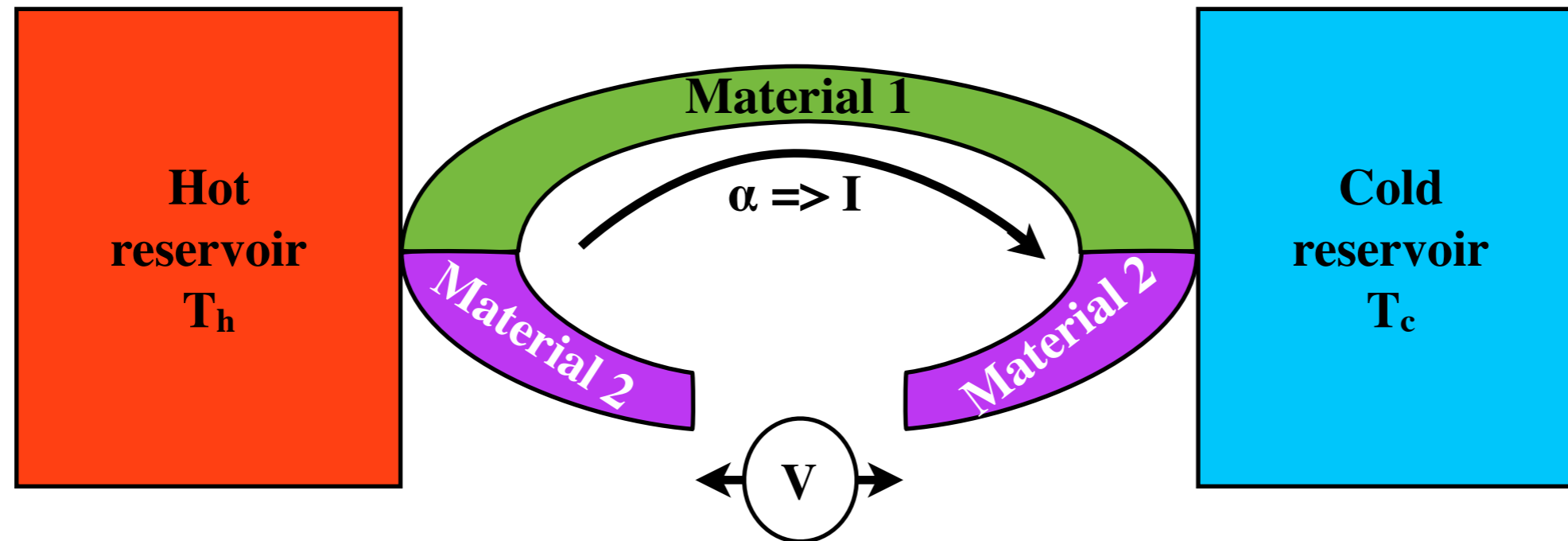
# The Peltier Coefficient

- Full derivation uses relaxation time approximation & Boltzmann equation
- $$\Pi = -\frac{1}{q} \int (\mathbf{E} - \mathbf{E}_F) \frac{\sigma(\mathbf{E})}{\sigma} d\mathbf{E}$$
- $$\sigma = \int \sigma(\mathbf{E}) d\mathbf{E} = q \int g(\mathbf{E}) \mu(\mathbf{E}) f(\mathbf{E}) [1 - f(\mathbf{E})] d\mathbf{E}$$
- This derivation works well for high temperatures ( $> 100$  K)
- At low temperatures phonon drag effects must be added

see H. Fritzsche, Solid State Comm. 9, 1813 (1971)



# The Seebeck Effect



● Open circuit voltage,  $V = \alpha (T_h - T_c) = \alpha \Delta T$

Seebeck coefficient,  $\alpha = \frac{dV}{dT}$  units: V/K

● Seebeck coefficient =  $\frac{1}{q}$  x entropy  $\left(\frac{Q}{T}\right)$  transported with charge carrier

# The Seebeck Coefficient

- Full derivation uses relaxation time approximation, Boltzmann equation

- $$\alpha = \frac{1}{qT} \left[ \frac{\langle \mathbf{E}\tau \rangle}{\langle \tau \rangle} - \mathbf{E}_F \right]$$

- $$\alpha = -\frac{k_B}{q} \int \frac{(\mathbf{E} - \mathbf{E}_F)}{k_B T} \frac{\sigma(\mathbf{E})}{\sigma} d\mathbf{E}$$

$$\sigma = \int \sigma(\mathbf{E}) d\mathbf{E} = q \int g(\mathbf{E}) \mu(\mathbf{E}) f(\mathbf{E}) [1 - f(\mathbf{E})] d\mathbf{E}$$

For electrons in the conduction band,  $E_c$  of a semiconductor

- $$\alpha = -\frac{k_B}{q} \left[ \frac{E_c - E_F}{k_B T} + \frac{\int_0^\infty \frac{(\mathbf{E} - E_c)}{k_B T} \sigma(\mathbf{E}) d\mathbf{E}}{\int_0^\infty \sigma(\mathbf{E}) d\mathbf{E}} \right] \quad \text{for } \mathbf{E} > E_c$$

see Mott and Jones (1958) and H. Fritzsche, Solid State Comm. 9, 1813 (1971)

# The Seebeck Coefficient for Metals

●  $f(1 - f) = -k_B T \frac{df}{dE}$

● Expand  $g(E)\mu(E)$  in Taylor's series at  $E = E_F$

● 
$$\alpha = -\frac{\pi^2}{3q} k_B^2 T \left[ \frac{d \ln(\mu(E)g(E))}{dE} \right]_{E=E_F} \quad \text{(Mott's formula)}$$

**Mott and Jones, 1958**

● i.e. Seebeck coefficient depends on the asymmetry of the current contributions above and below  $E_F$

Using the energy-independent scattering approximation:

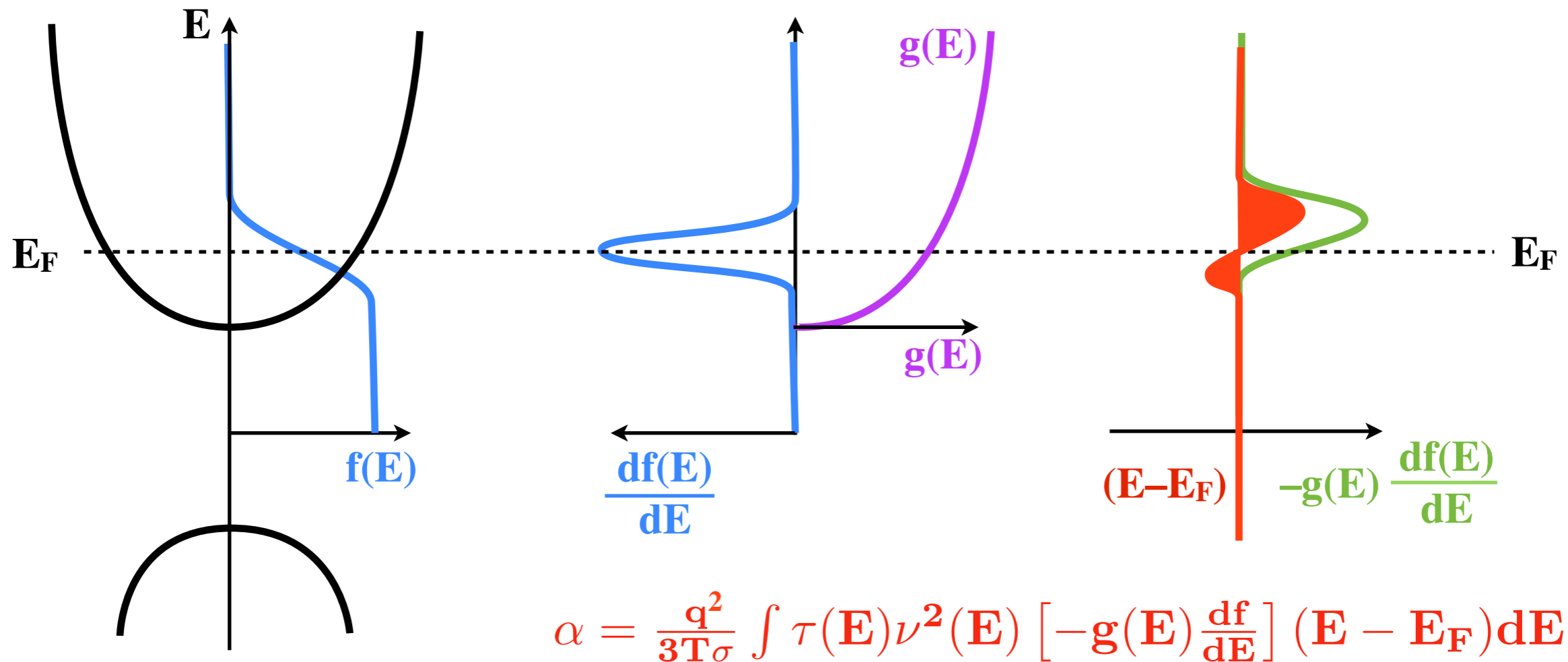
● 
$$\alpha = -\frac{8\pi^2 k_B^2}{3eh^2} m^* T \left( \frac{\pi}{3n} \right)^{\frac{2}{3}} (1 + C) \quad \text{n=carrier density}$$

*M. Cutler et al., Phys. Rev. 133, A1143 (1964)*

# The Physics of the Thermoelectric Effect

- If we ignore energy dependent scattering (i.e.  $\tau = \tau(E)$ ) then from Ziman

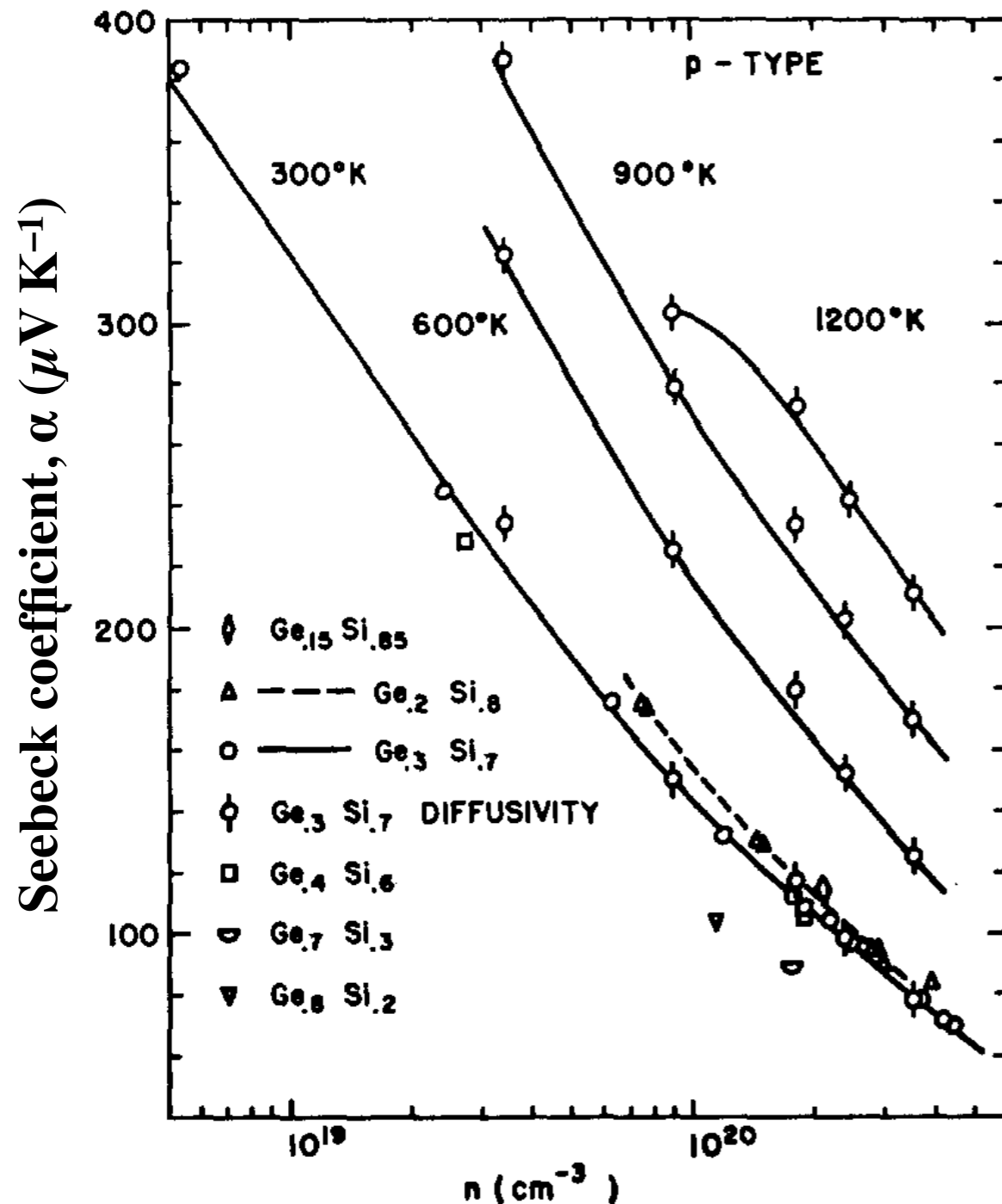
$$\sigma = \frac{q^2}{3} \int \tau(\mathbf{E}) v^2(\mathbf{E}) \left[ -g(\mathbf{E}) \frac{df}{dE} \right] dE$$



$$\alpha = \frac{q^2}{3T\sigma} \int \tau(\mathbf{E}) v^2(\mathbf{E}) \left[ -g(\mathbf{E}) \frac{df}{dE} \right] (E - E_F) dE$$

- Thermoelectric power requires asymmetry in red area under curve

# Semiconductor Example: SiGe Alloys

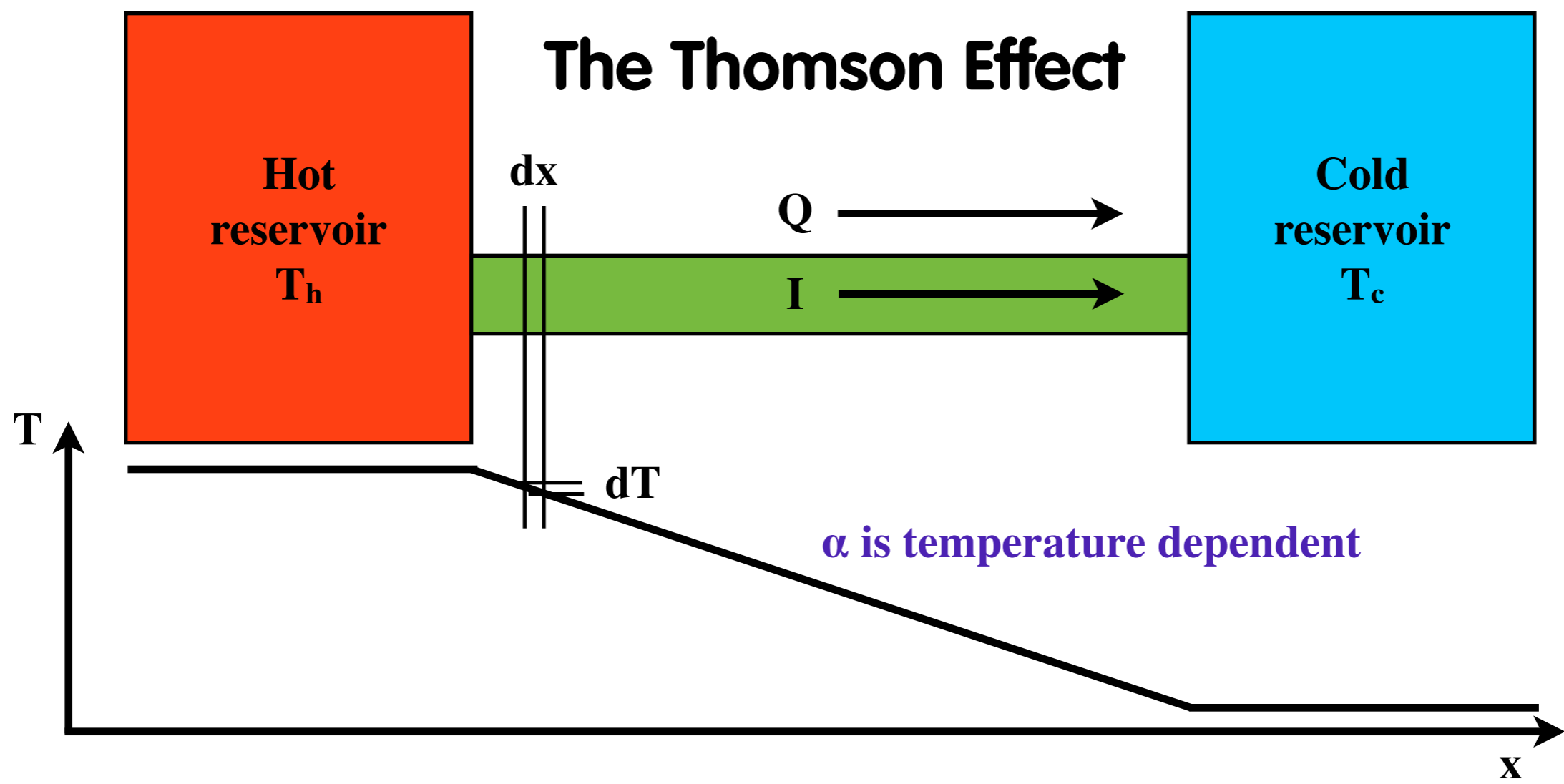


J.P. Dismukes et al., J. Appl. Phys. 35, 2899 (1964)

- Mott criteria  $\sim 2 \times 10^{18} \text{ cm}^{-3}$
- Degenerately doped p- $\text{Si}_{0.7}\text{Ge}_{0.3}$
- $\alpha$  decreases for higher  $n$
- For SiGe,  $\alpha$  increases with  $T$

$$\alpha = \frac{8\pi^2 k_B^2}{3eh^2} m^* T \left( \frac{\pi}{3n} \right)^{\frac{2}{3}}$$

# The Thomson Effect



●  $\frac{dQ}{dx} = \beta I \frac{dT}{dx}$

Thomson coefficient,  $\beta$        $dQ = \beta I dT$

units: V/K

# The Kelvin Relationships

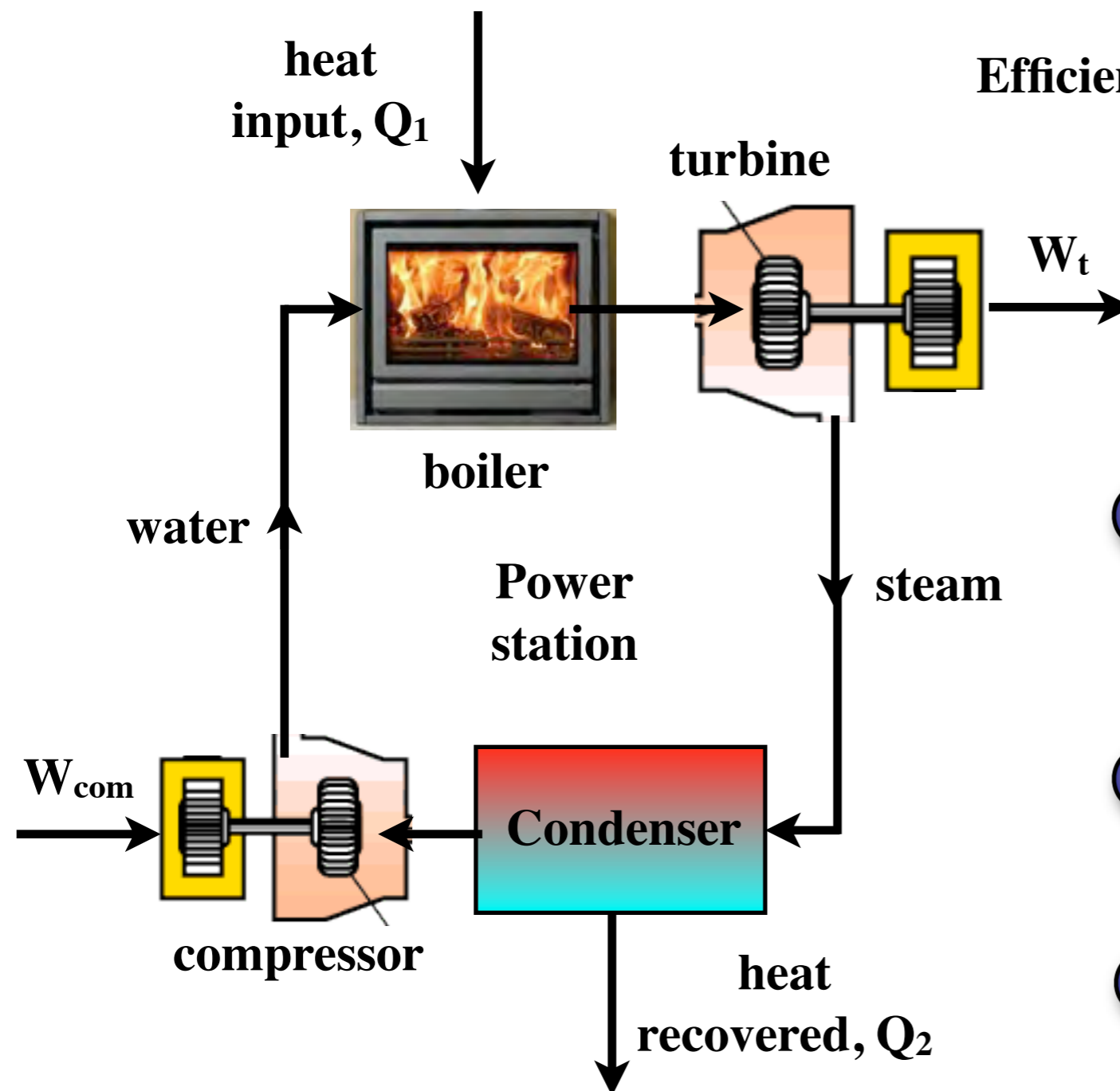
- Derived using irreversible thermodynamics

$$\Pi = \alpha T$$

$$\beta = T \frac{d\alpha}{dT}$$

- These relationships hold for all materials
- Seebeck,  $\alpha$  is easy to measure experimentally
- Therefore measure  $\alpha$  to obtain  $\Pi$  and  $\beta$

# Thermodynamic Efficiency for Power Stations



$$\text{Efficiency} = \eta = \frac{\text{net work output}}{\text{heat input}}$$

$$= \frac{W_t - W_{com}}{Q_1}$$

● 1<sup>st</sup> law thermodynamics

$$(Q_1 - Q_2) - (W_t - W_{com}) = 0$$

●  $\eta = \frac{Q_1 - Q_2}{Q_1}$

●  $\eta = 1 - \frac{Q_2}{Q_1}$



# Carnot Efficiency

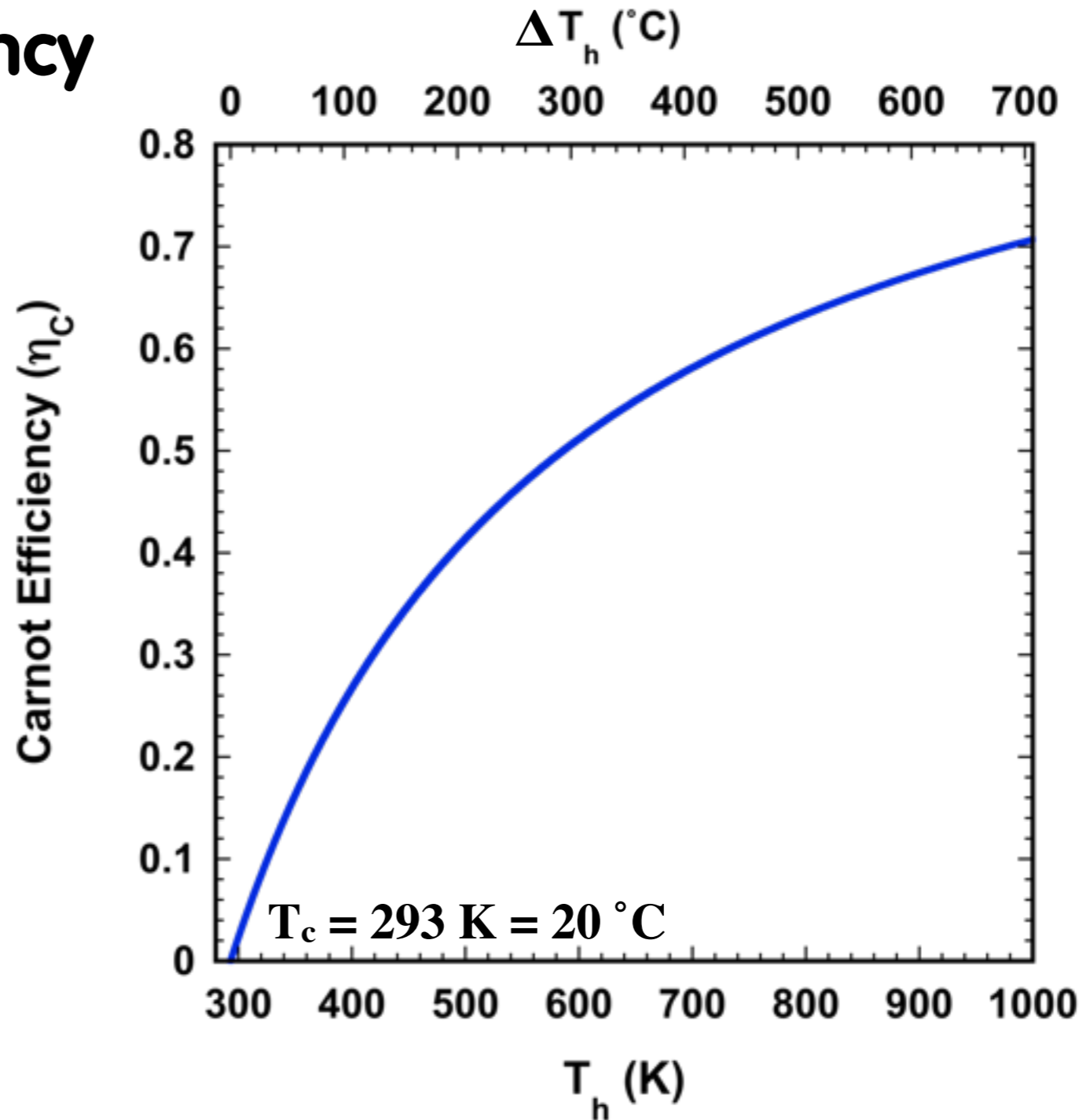
Efficiency =

$$\eta = \frac{\text{net work output}}{\text{heat input}}$$

$$\eta = 1 - \frac{Q_2}{Q_1}$$

Carnot: maximum  $\eta$  only depends on  $T_c$  and  $T_h$

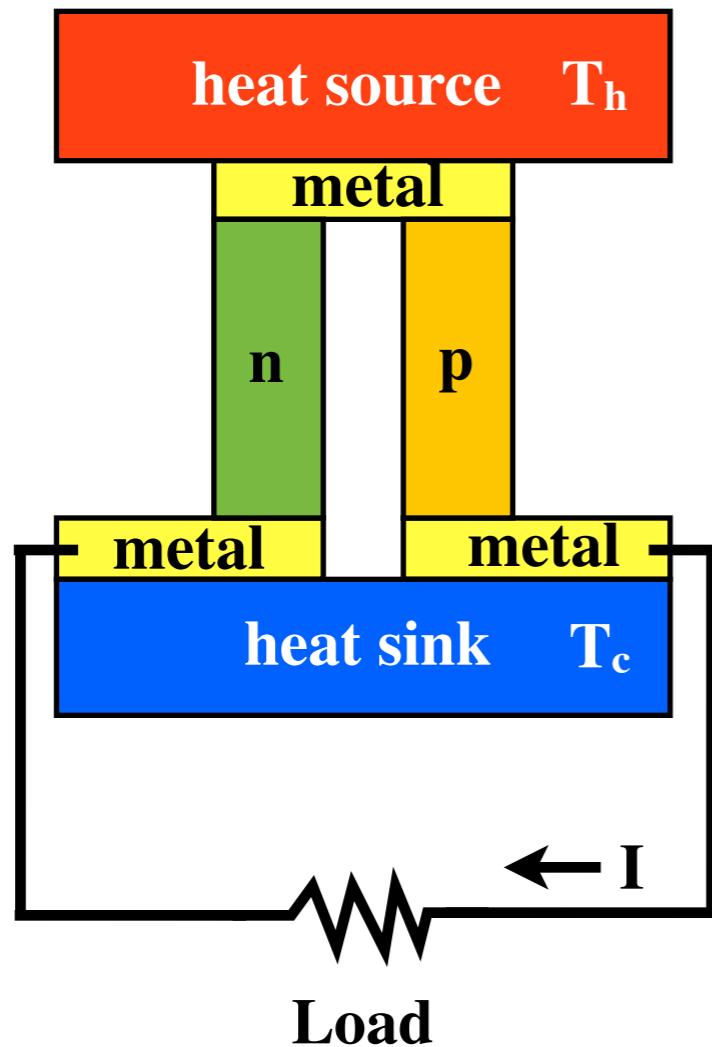
$$\eta_c = 1 - \frac{T_c}{T_h}$$



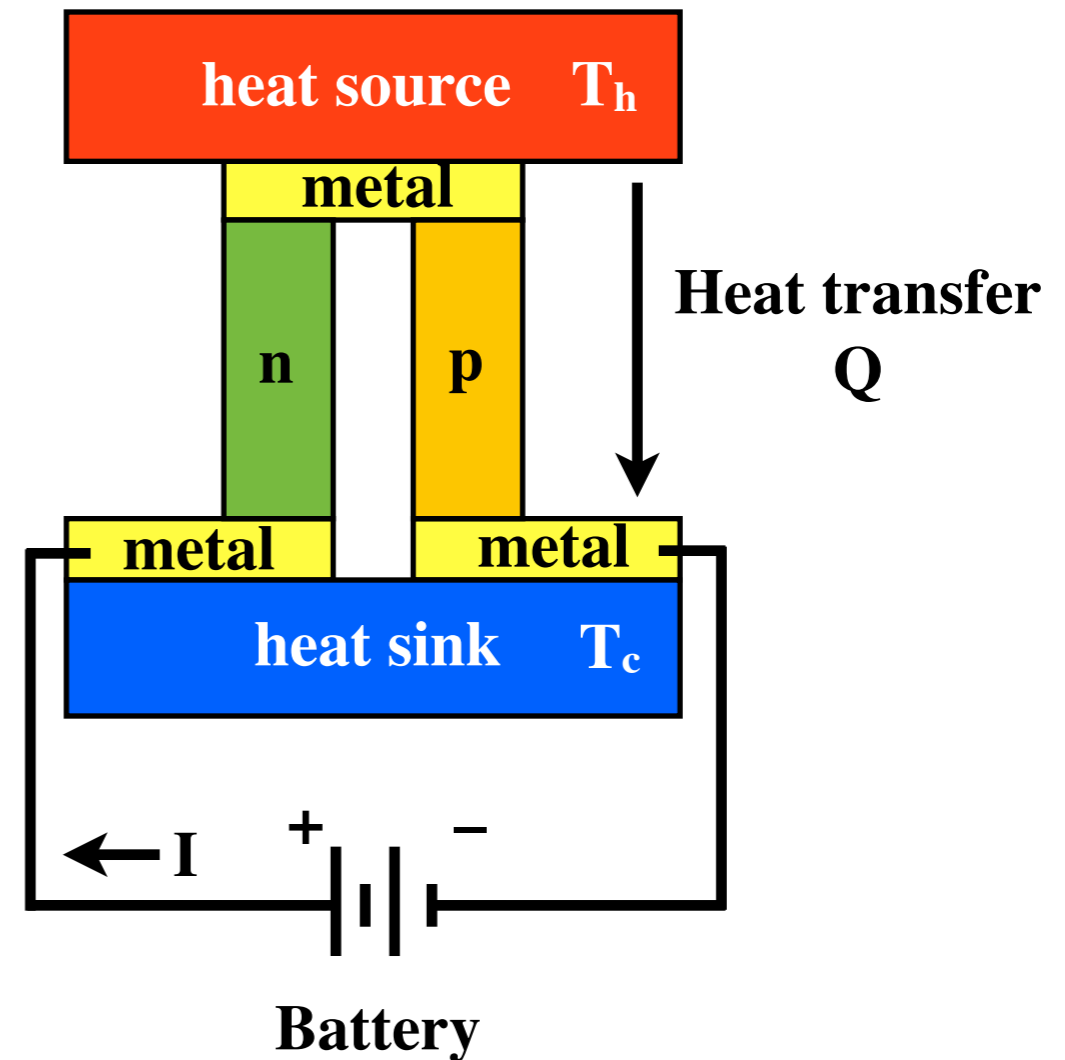
**2<sup>nd</sup> law thermodynamics: no system operating in closed cycle can convert all the heat absorbed from a heat reservoir into the same amount of work**

# Semiconductors and Thermoelectrics

Seebeck effect:  
electricity  
generation

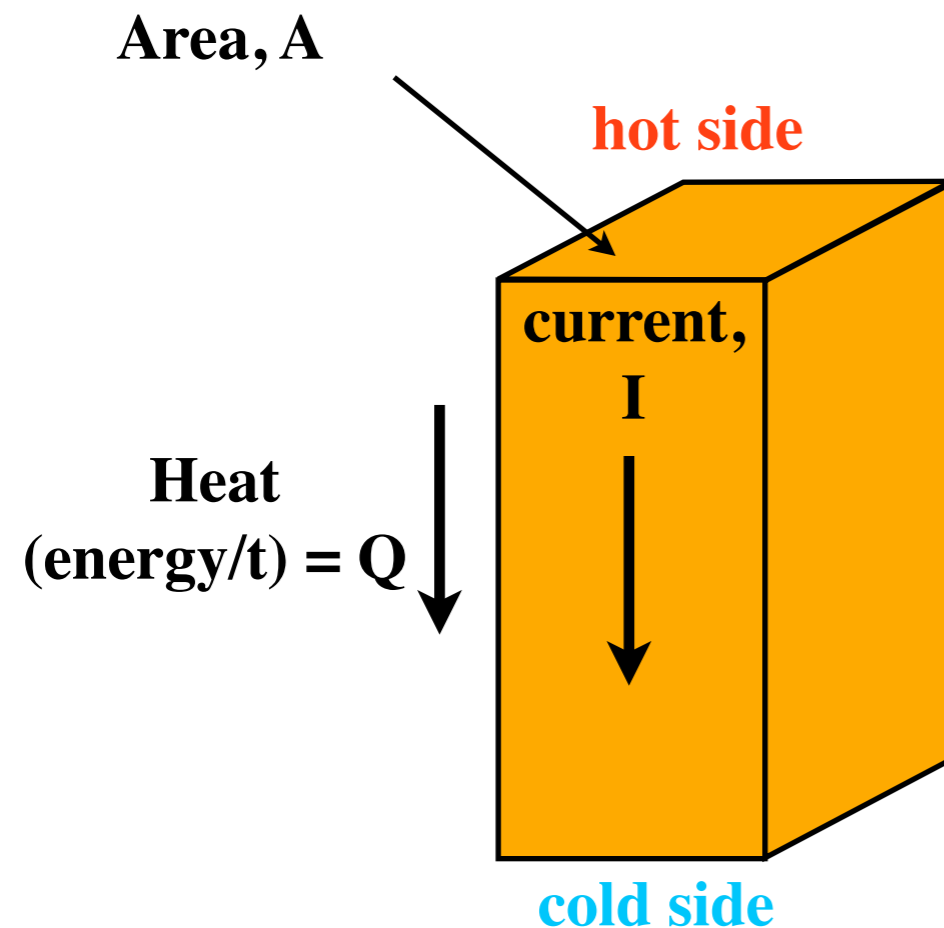


Peltier effect:  
electrical cooling  
i.e. heat pump



# Peltier Effect, Heat Flux and Temperature

- If a current of  $I$  flows through a thermoelectric material between hot and cold reservoirs:



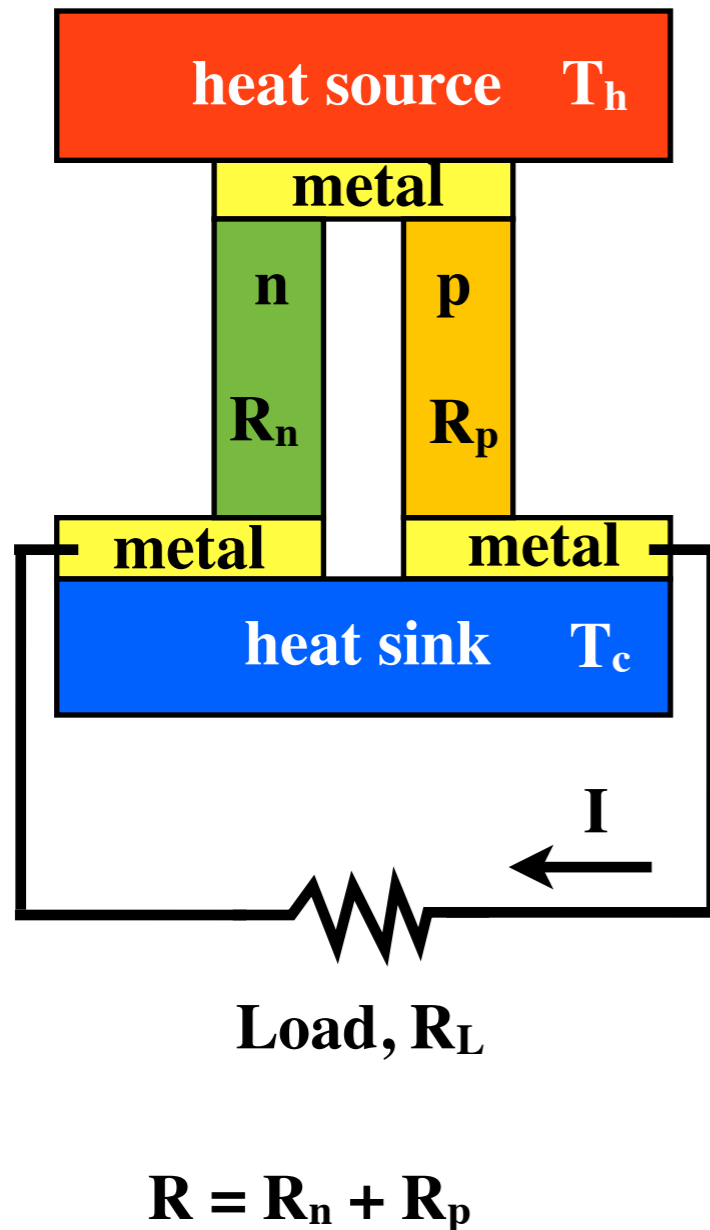
- Heat flux per unit area =  
( = Peltier + Fourier )

- $$\frac{Q}{A} = \Pi J - \kappa \nabla T$$

but  $\Pi = \alpha T$  and  $J = \frac{I}{A}$

$$Q = \alpha IT - \kappa A \nabla T$$

# Conversion Efficiency

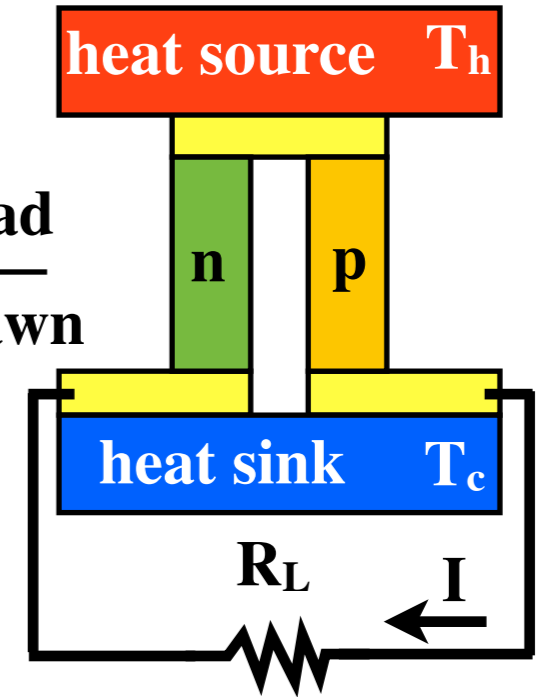


- $\eta = \frac{\text{power supplied to load}}{\text{heat absorbed at hot junction}}$
- Power to load (Joule heating) =  $I^2 R_L$
- Heat absorbed at hot junction = Peltier heat + heat withdrawn from hot junction
- Peltier heat =  $\Pi I = \alpha I T_h$
- $I = \frac{\alpha(T_h - T_c)}{R + R_L}$  (Ohms Law)
- Heat withdrawn from hot junction  
 $= \kappa A (T_h - T_c) - \frac{1}{2} I^2 R$   
↑  
 NB half Joule heat returned to hot junction

# Conversion Efficiency

$$\eta = \frac{\text{power supplied to load}}{\text{heat absorbed at hot junction}} = \frac{\text{power supplied to load}}{\text{Peltier} + \text{heat withdrawn}}$$

$$\eta = \frac{I^2 R_L}{\alpha I T_h + \kappa A (T_h - T_c) - \frac{1}{2} I^2 R}$$



For maximum value  $\frac{d\eta}{d(\frac{R_L}{R})} = 0$

$$T = \frac{1}{2}(T_h + T_c)$$

$$\eta_{\max} = \frac{T_h - T_c}{T_h} \frac{\sqrt{1 + ZT} - 1}{\sqrt{1 + ZT} + \frac{T_c}{T_h}}$$

where  $Z = \frac{\alpha^2}{R\kappa A} = \frac{\alpha^2 \sigma}{\kappa}$

= Carnot x Joule losses and irreversible processes

# Thermoelectric Power Generating Efficiency

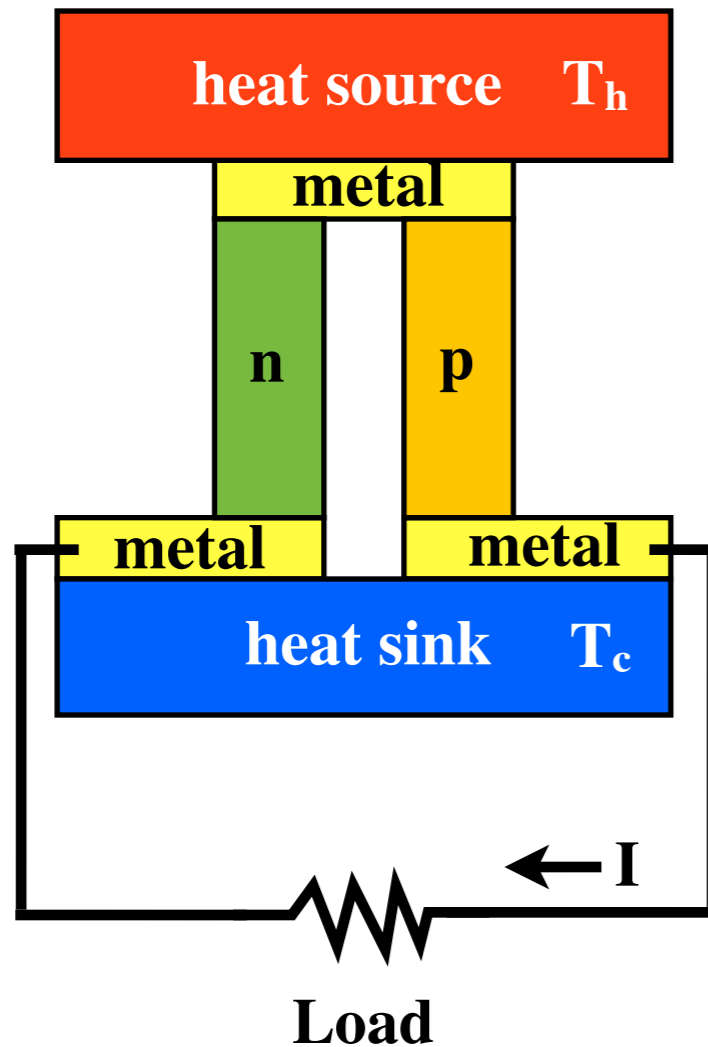
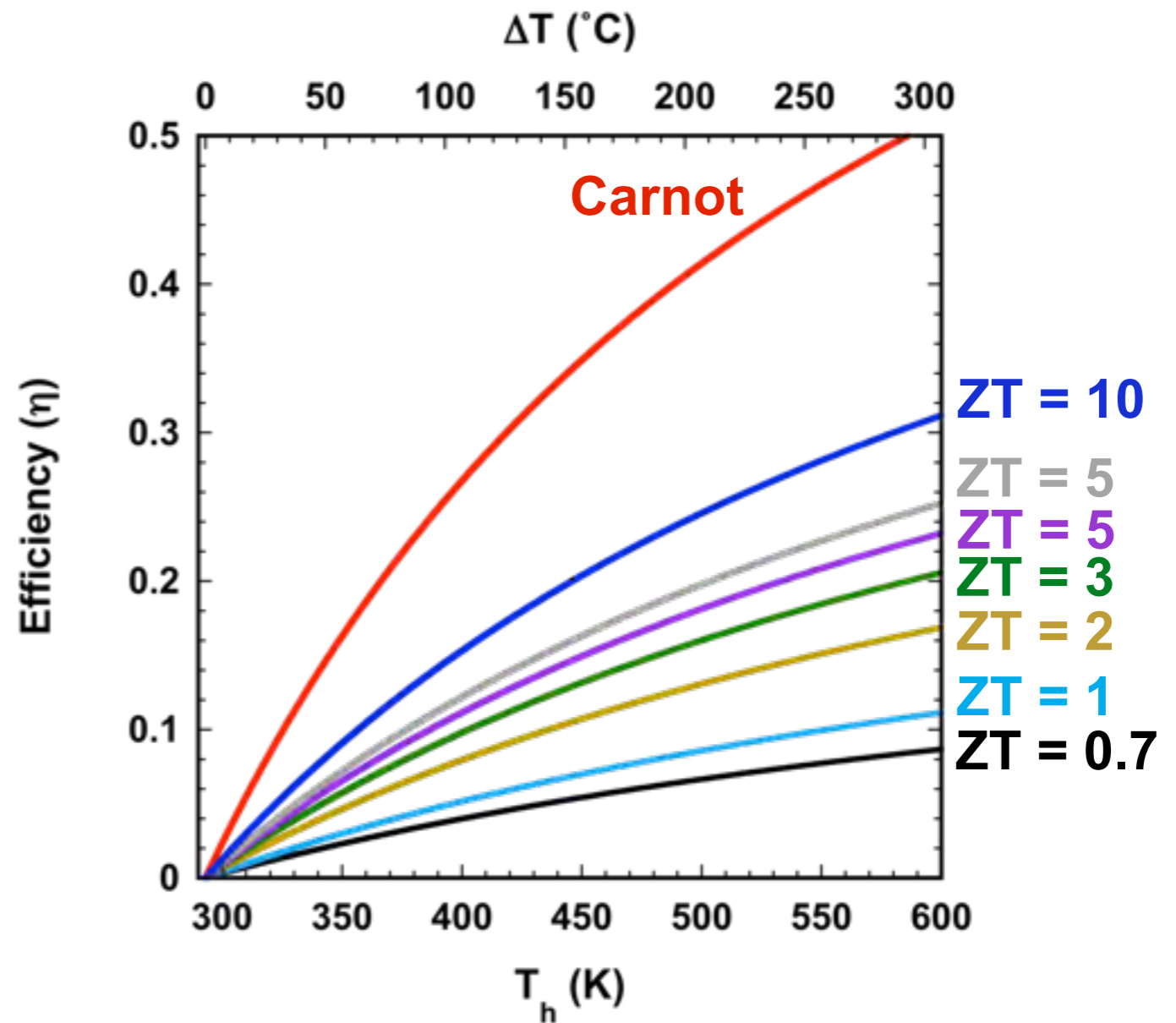


Figure of merit

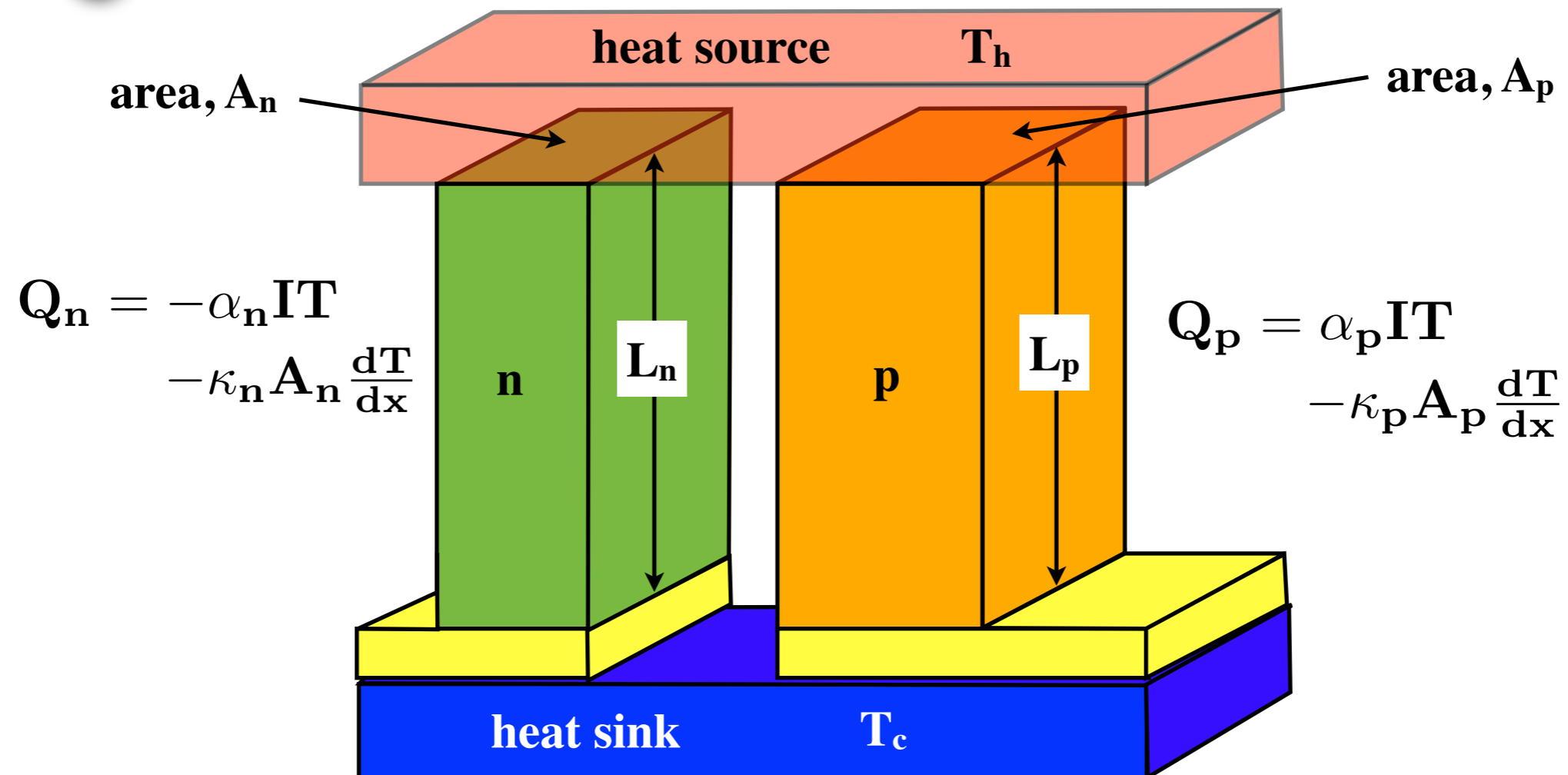
$$ZT = \frac{\alpha^2 \sigma}{\kappa} T$$

$$\eta = \frac{\Delta T}{T_h} \frac{\sqrt{1+ZT}-1}{\sqrt{1+ZT} + \frac{T_c}{T_h}}$$



# Heat Transfer in Thermoelectric Element

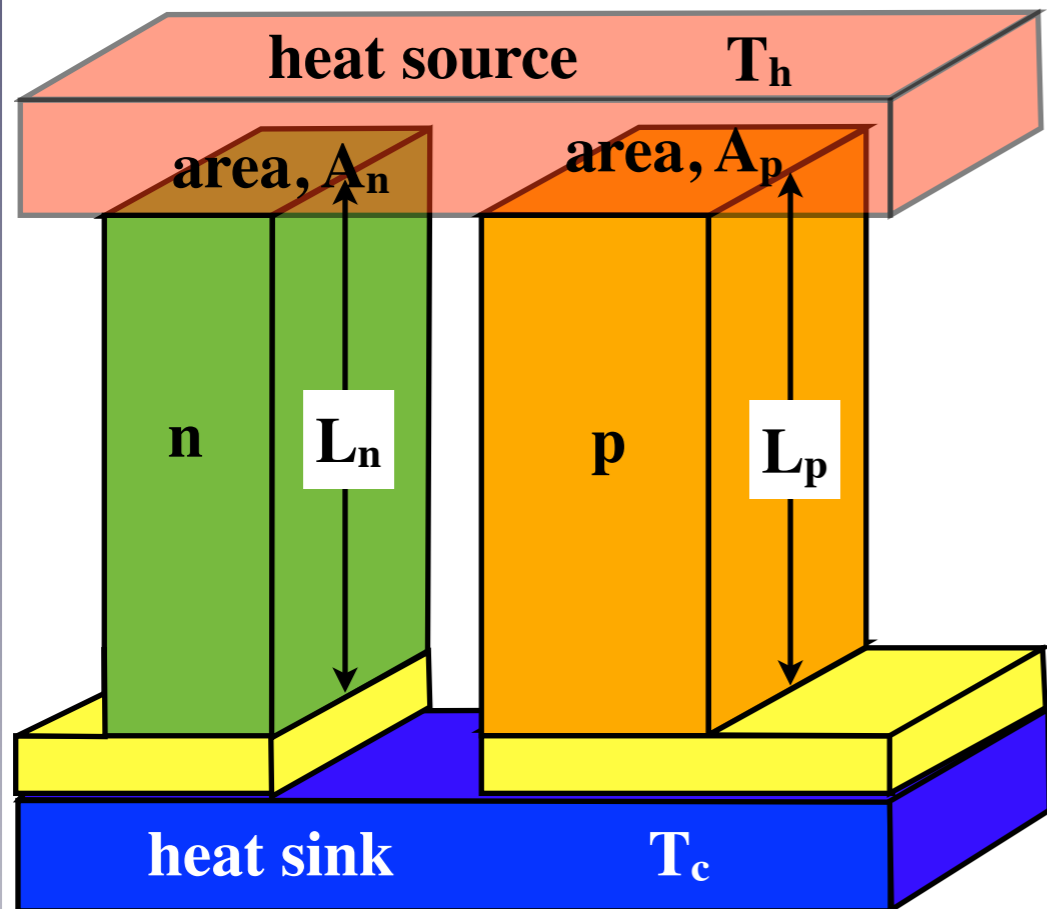
- But n-type and p-type materials are seldom identical



- $Z$  for a couple depends on relative dimensions

- $Z$  is maximum for  $\frac{L_n A_p}{L_p A_n} = \sqrt{\frac{\sigma_n \kappa_n}{\sigma_p \kappa_p}}$

# Maximising ZT for an Unbalanced Couple



$$\frac{L_n A_p}{L_p A_n} = \sqrt{\frac{\sigma_n \kappa_n}{\sigma_p \kappa_p}}$$

$$ZT = \frac{(\alpha_p - \alpha_n)^2 T}{\left[ \sqrt{\frac{\kappa_p}{\sigma_p}} + \sqrt{\frac{\kappa_n}{\sigma_n}} \right]}$$

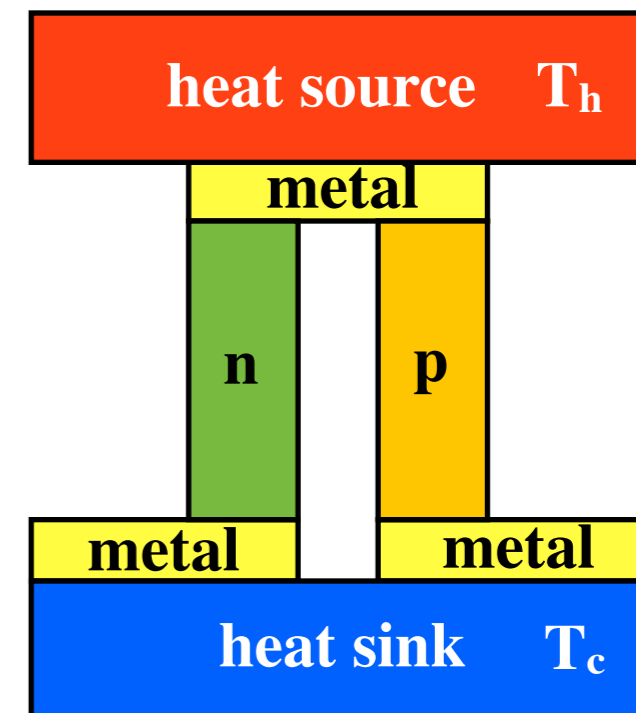


We need good ZT for both n- and p-type semiconductors

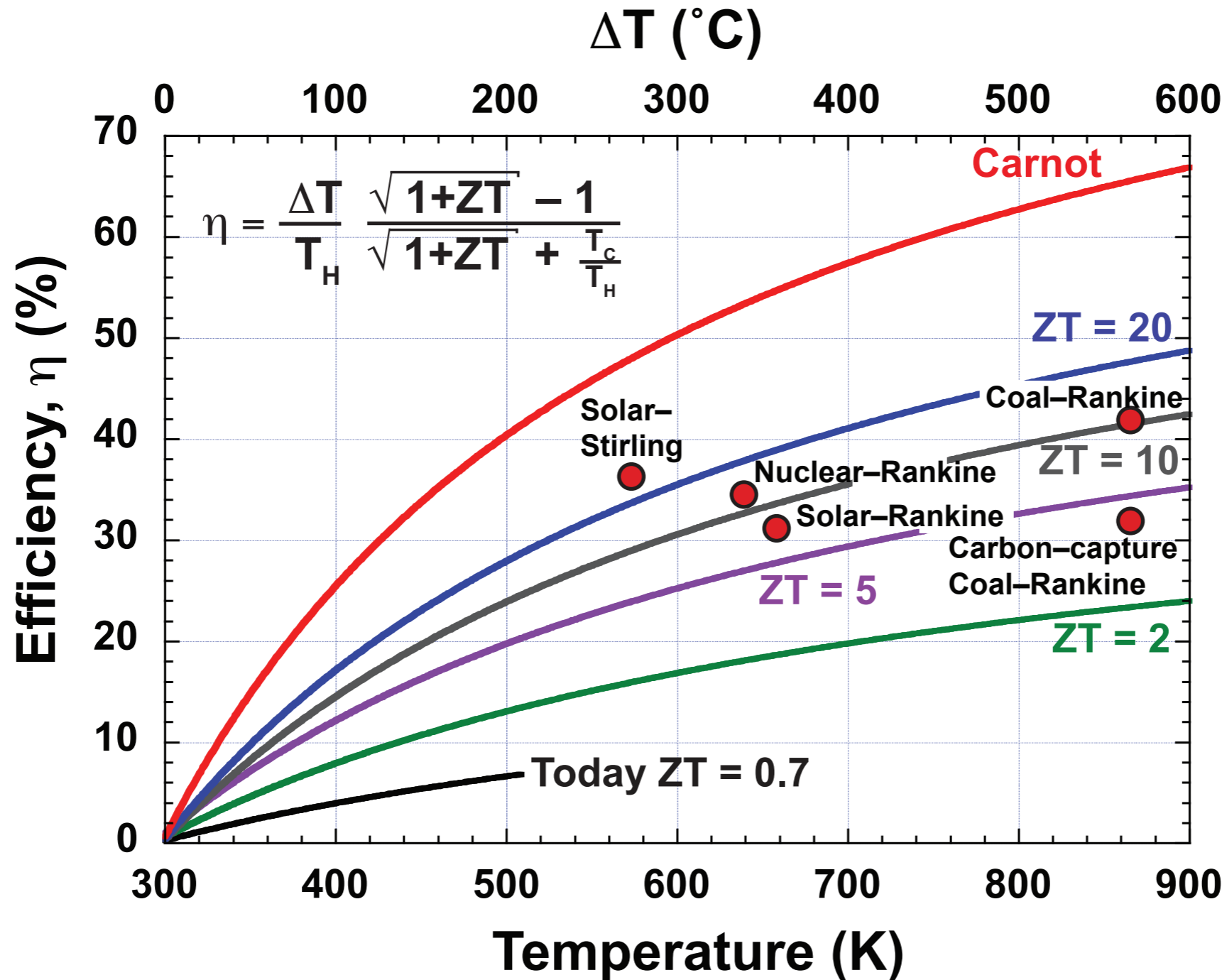


# Maximum Temperature Drop

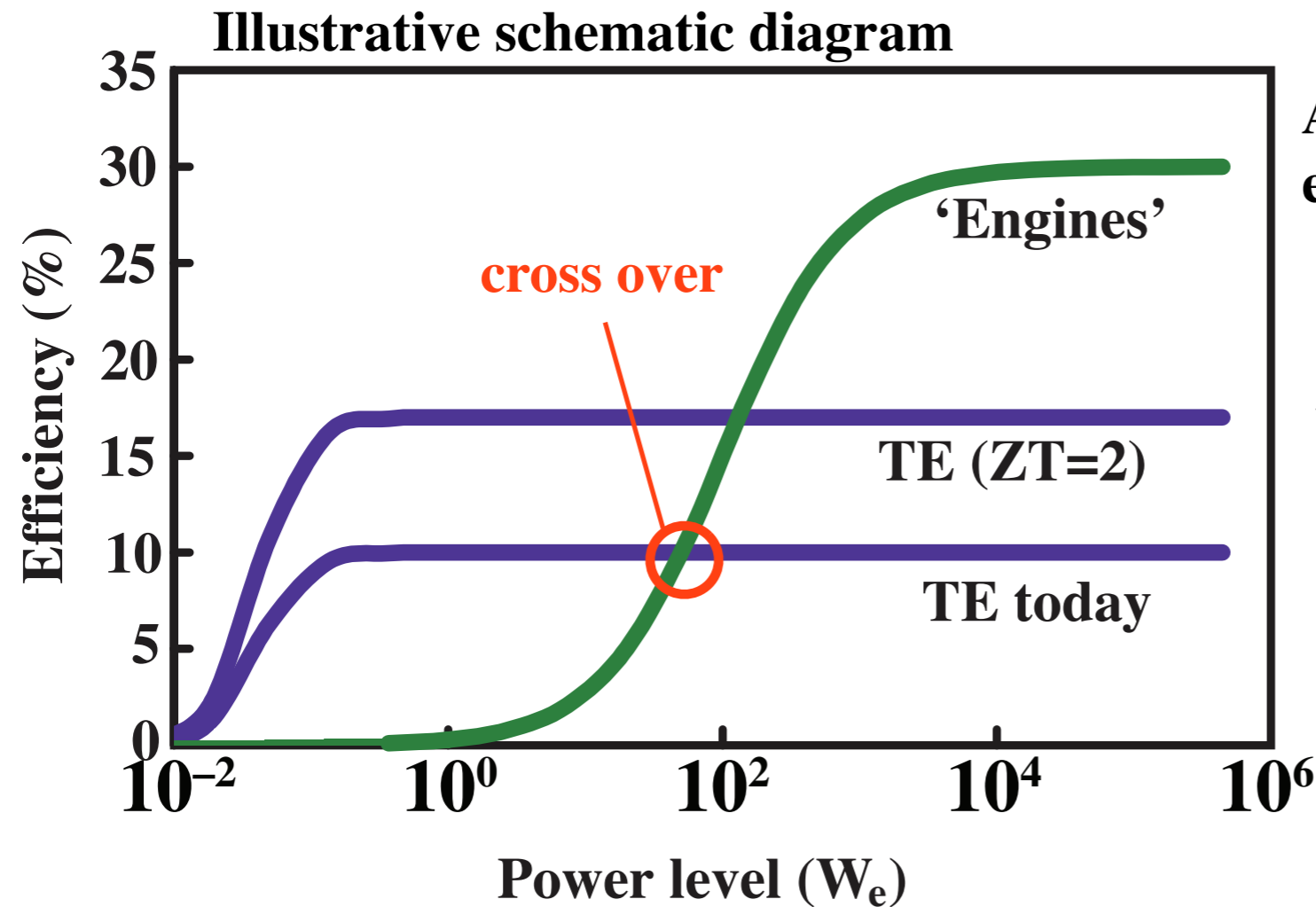
- As the system has thermal conductivity  $\kappa$  a maximum  $\Delta T$  which can be sustained across a module is limited due to heat transport
- $$\Delta T_{\max} = \frac{1}{2} Z T_c^2$$
- The efficiency cannot be increased indefinitely by increasing  $T_h$
- The thermal conductivity also limits maximum  $\Delta T$  in Peltier coolers
- Higher  $\Delta T_{\max}$  requires better  $Z$  materials



# Thermodynamic Efficiency



# Power Generation From Macro to Micro



At large scale, thermodynamic engines more efficient than TE

ZT average for both n and p over all temperature range

Diagram assumes high T



At the mm and  $\mu\text{m}$  scale with powers  $\ll 1\text{W}$ , thermoelectrics are more efficient than thermodynamic engines (Reynolds no. etc..)

*C.B. Vining, Nature Mat. 8, 83 (2009)*

# Thermal Conductivity of Bulk Materials

- Both the lattice and electron current can contribute to heat transfer

thermal conductivity = electron contribution + phonon contribution  
= (electrical conductivity) + (lattice contributions)

$$\kappa = \kappa_{el} + \kappa_{ph}$$

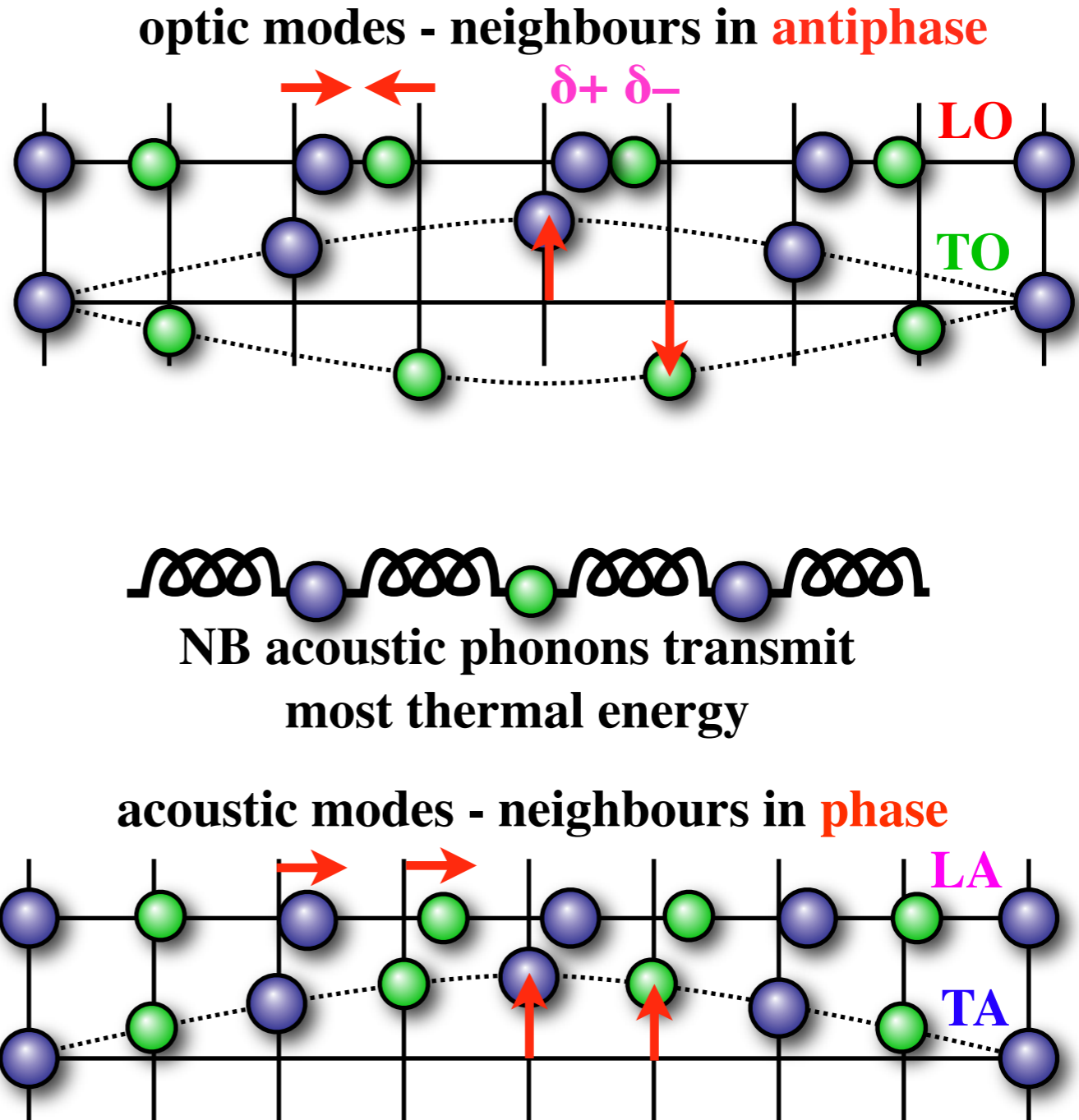
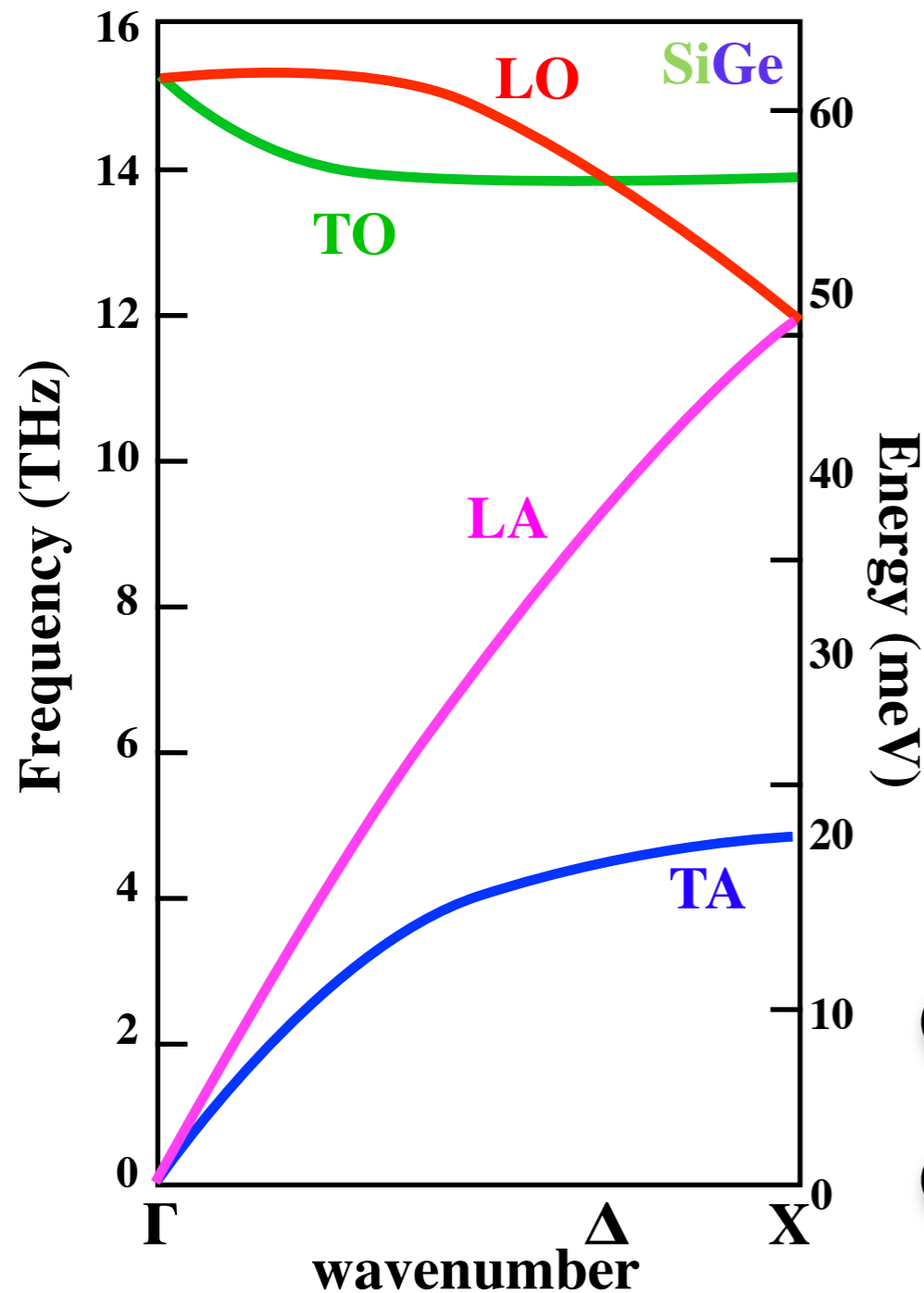
- For low carrier densities in semiconductors (non-degenerate)  $\kappa_{el} \ll \kappa_{ph}$

- For high carrier densities in semiconductors (degenerate)  $\kappa_{el} \gg \kappa_{ph}$

- Good thermoelectric materials should ideally have  $\kappa_{el} \ll \kappa_{ph}$

i.e. electrical and thermal conductivities are largely decoupled

# Phonons: Lattice Vibration Heat Transfer



# Thermal Conductivity

Lattice contribution:

$$\bullet \quad \kappa_{\text{ph}} = \frac{k_{\text{B}}}{2\pi^2} \left( \frac{k_{\text{B}}}{\hbar} \right)^3 T^3 \int_0^{\frac{\theta_{\text{D}}}{T}} \frac{\tau_{\text{c}}(\mathbf{x}) \mathbf{x}^4 e^{\mathbf{x}}}{v(\mathbf{x})(e^{\mathbf{x}} - 1)^2} d\mathbf{x}$$

$\theta_{\text{D}}$  = Debye temperature (640 K for Si)

$$\mathbf{x} = \frac{\hbar\omega}{k_{\text{B}}T}$$

$\tau_{\text{c}}$  = combined phonon scattering time

$v(\mathbf{x})$  = velocity

*J. Callaway, Phys. Rev. 113, 1046 (1959)*

Electron (hole) contribution:

$$\bullet \quad \kappa_{\text{el}} = \frac{\sigma}{q^2 T} \left[ \frac{\langle \tau \rangle \langle \mathbf{E}^2 \tau \rangle - \langle \mathbf{E} \tau \rangle^2}{\langle \tau^3 \rangle} \right]$$

$\tau(\mathbf{E})$  = total electron momentum relaxation time

*B. R. Nag, Electron Transport in Compound Semiconductors,  
(Springer-Verlag, New York USA, 1980)*

# Wiedemann-Franz Law

- Empirical law from experimental observation that  $\frac{\kappa}{\sigma T} = \text{constant}$  for metals
- Drude model's great success was an explanation of Wiedemann-Franz
- Drude model assumes bulk of thermal transport by conduction electrons in metals
- Success fortuitous: two factors of 100 cancel to produce the empirical result from the Drude theory
- Incorrect assumption: classical gas laws cannot be applied to electron gas

# Wiedemann-Franz Law for Metals

- In metals, the thermal conductivity is dominated by  $\kappa_{el}$

$$\therefore \frac{\sigma T}{\kappa} = \frac{3}{\pi^2} \left( \frac{q}{k_B} \right)^2 = \frac{1}{L}$$

$$L = \text{Lorentz number} \\ = 2.45 \times 10^{-8} \text{ W}\cdot\Omega\text{K}^{-2}$$

$$ZT = \frac{3}{\pi^2} \left( \frac{q\alpha}{k_B} \right)^2 = 4.09 \times 10^7 \alpha^2$$

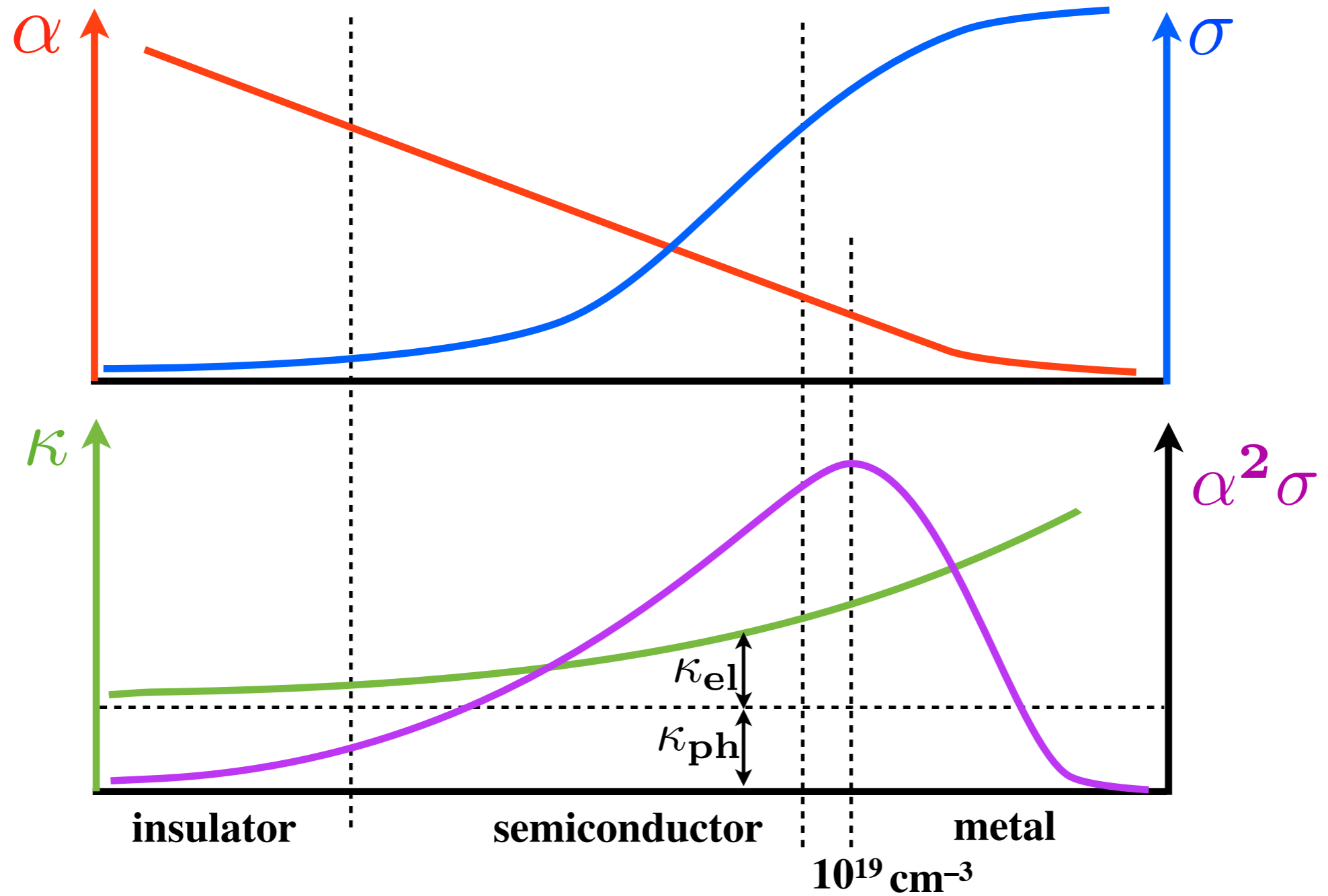
$$\text{for } \kappa_{el} \gg \kappa_{ph}$$

## Exceptions:

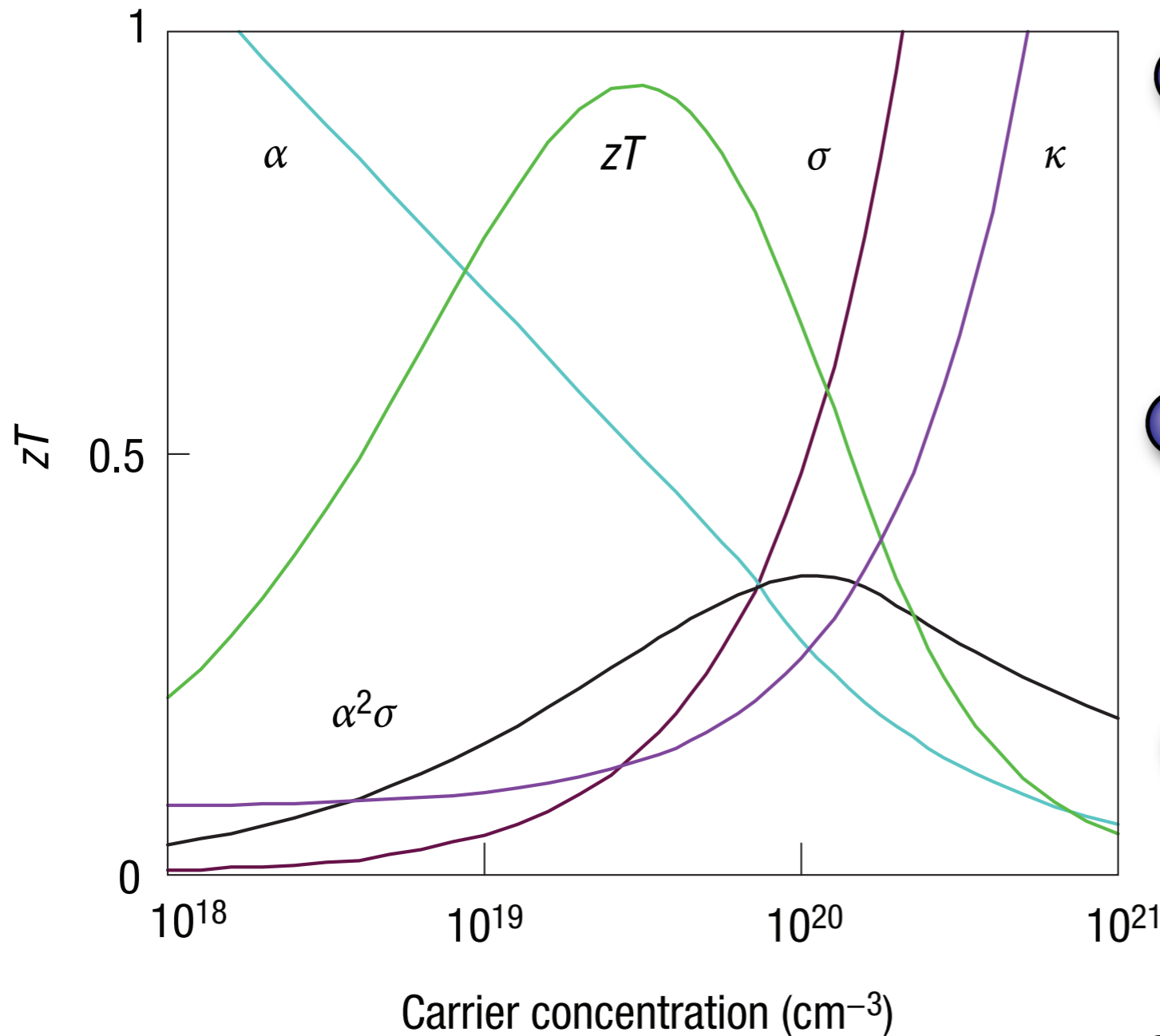
- most exceptions systems with  $\kappa_{el} \ll \kappa_{ph}$
- some pure metals at low temperatures
- certain alloys where small  $\kappa_{el}$  results in significant  $\kappa_{ph}$  contribution
- certain low dimensional structures where  $\kappa_{ph}$  can dominate



# Thermoelectric Effect vs Doping of Semiconductors



# Bi<sub>2</sub>Te<sub>3</sub> ZT Optimisation Through Doping



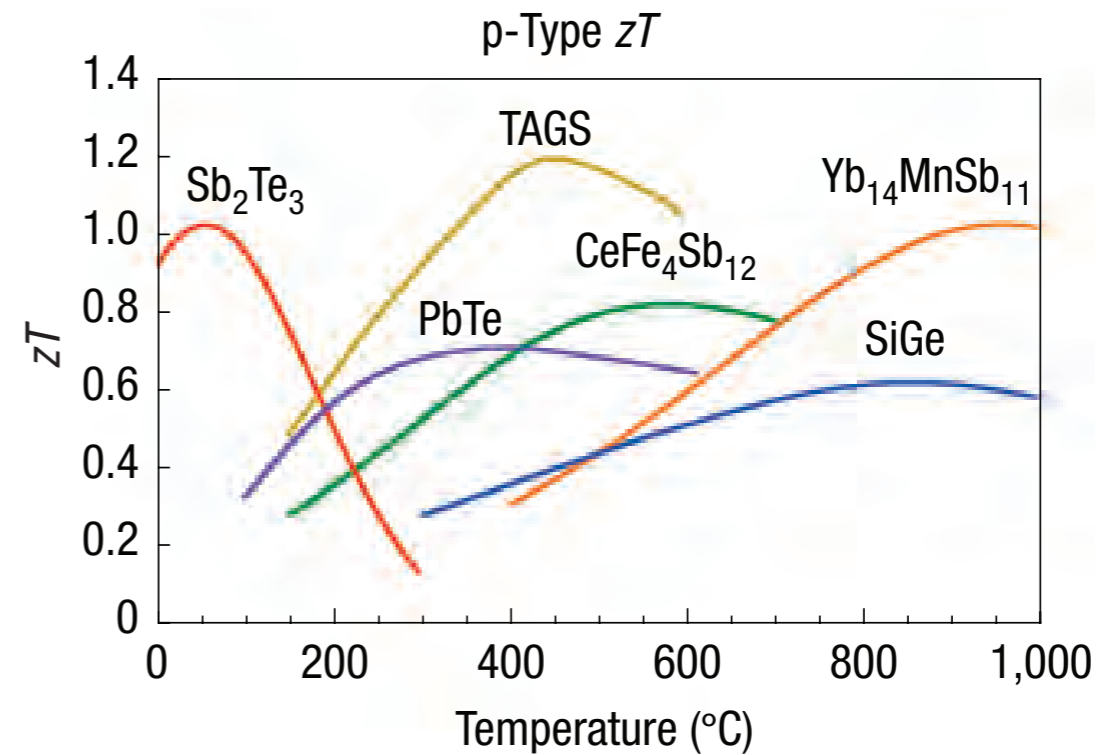
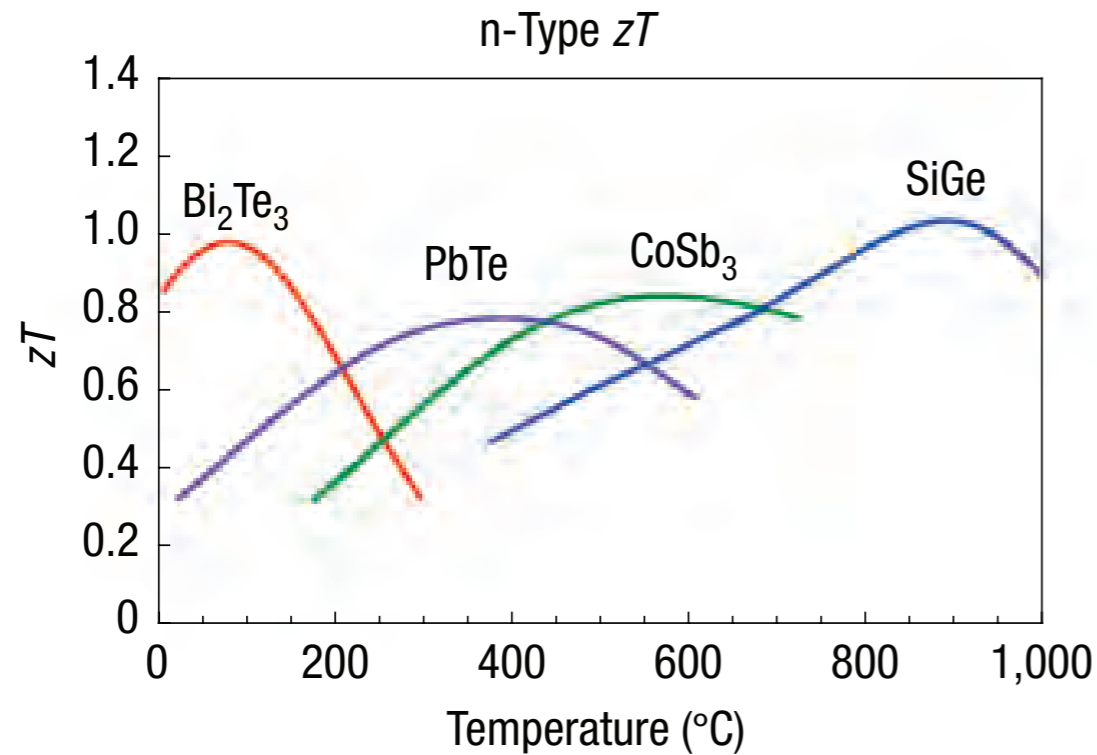
● Maximum ZT requires compromises with  $\alpha$ ,  $\sigma$  &  $\kappa$

● Limited by Wiedemann-Franz Law

● Maximum ZT  $\sim 1$  at  $\sim 100^\circ\text{C}$

*G.J. Snyder et al., Nature Mat. 7, 105 (2008)*

# Bulk Thermoelectric Materials Performance



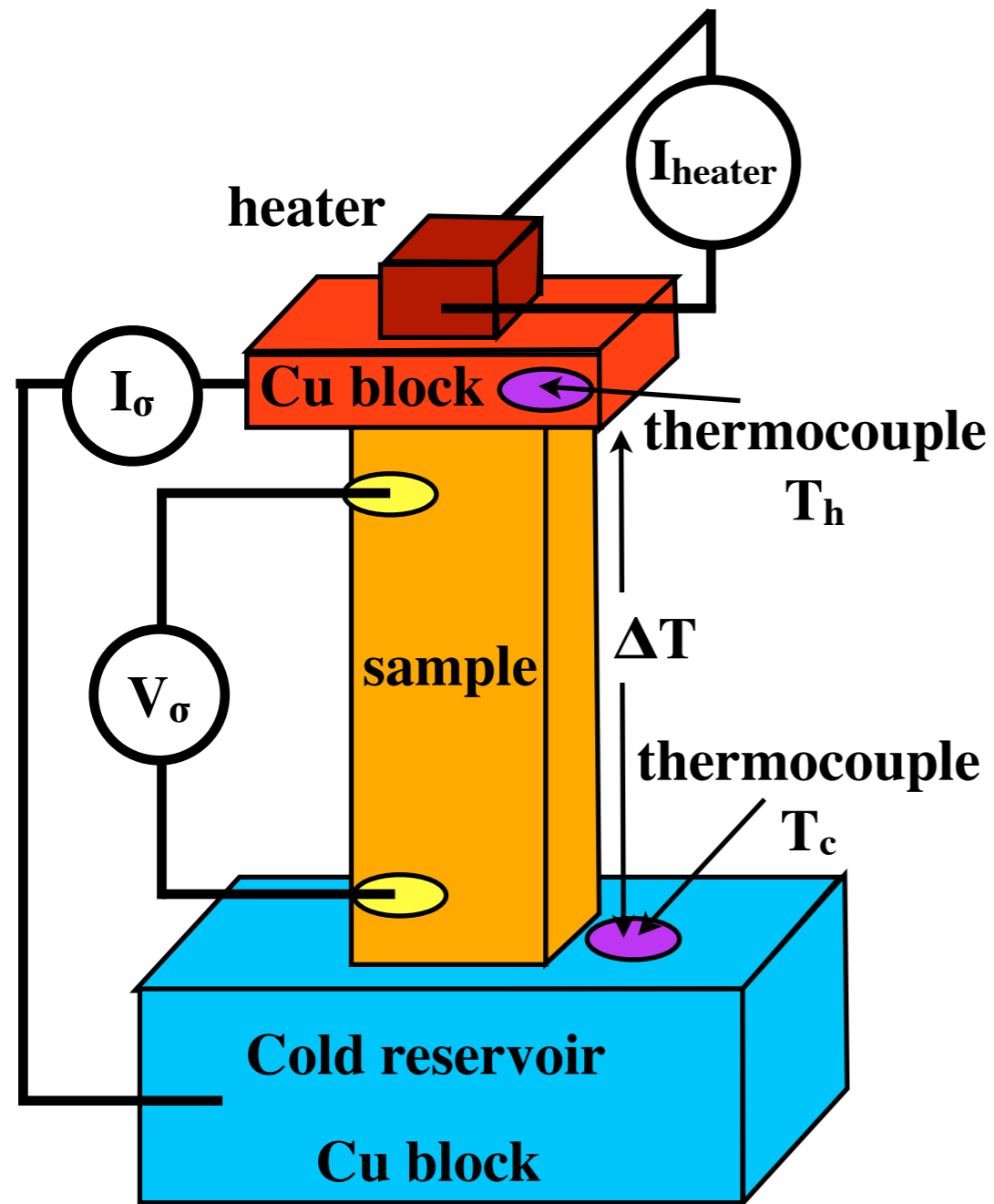
*Nature Materials 7, 105 (2008)*

- Bulk n-Bi<sub>2</sub>Te<sub>3</sub> and p-Sb<sub>2</sub>Te<sub>3</sub> used in most commercial Peltier coolers
- Bulk Si<sub>1-x</sub>Ge<sub>x</sub> (x~0.2 to 0.3) used for high temperature satellite applications
- ZT in bulk materials limited by Wiedemann-Franz law

# Measuring $\alpha$ , $\kappa$ , $\sigma$ and ZT

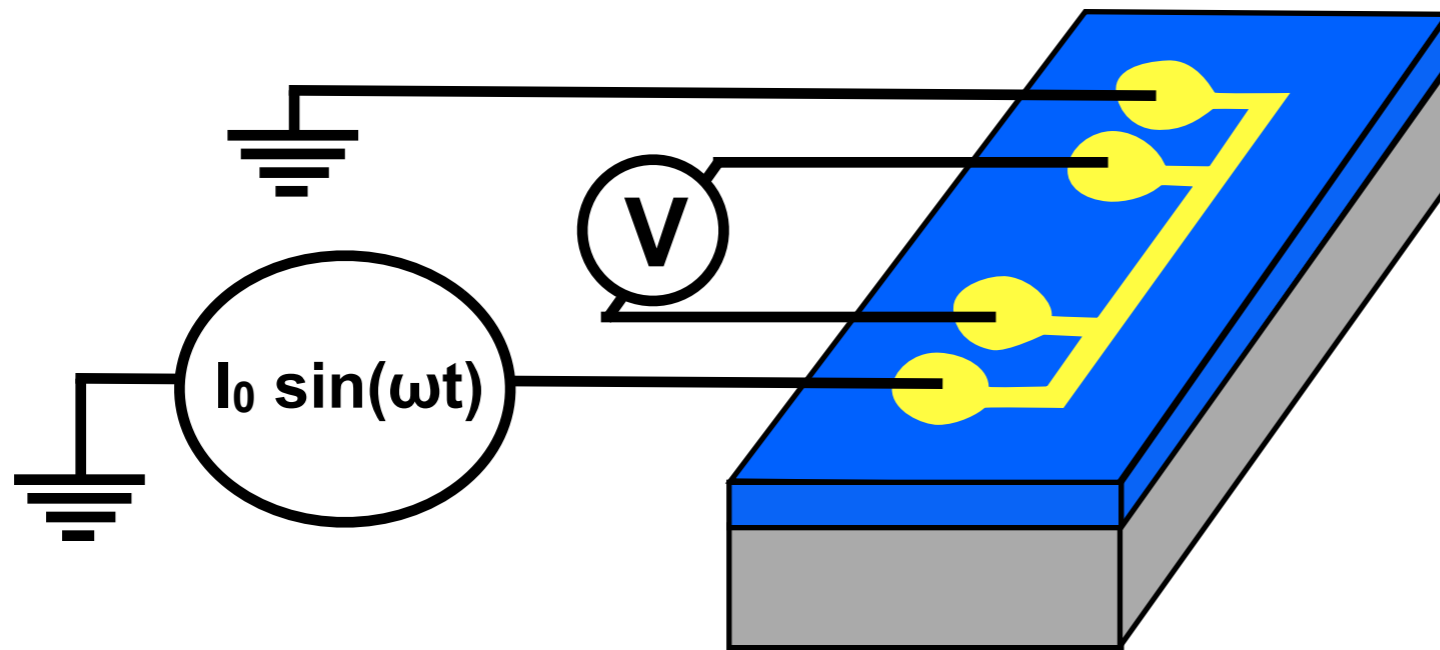
- $\sigma$  can be determined to  $> 4$  significant figures without difficulty
- Seebeck voltage can be measured to  $> 4$  significant figures but temperature is more difficult
- Measuring heat flow accurately is extremely difficult i.e.  $\kappa$
- The result is that measurements of ZT can have large uncertainties
- Care needs to be taken in measuring  $\alpha$ ,  $\sigma$ ,  $\kappa$  and ZT

# Measuring Seebeck Coefficient



- Physically heat one side of sample
- Cold sink at the other side of sample
- Thermocouples top and bottom to measure  $\Delta T$
- 4 terminal electrical measurements

# 3 $\omega$ Thermal Conductivity Measurements



$$I \sim \omega$$

$$T \sim I^2 \sim 2\omega$$

$$R \sim T \sim 2\omega$$

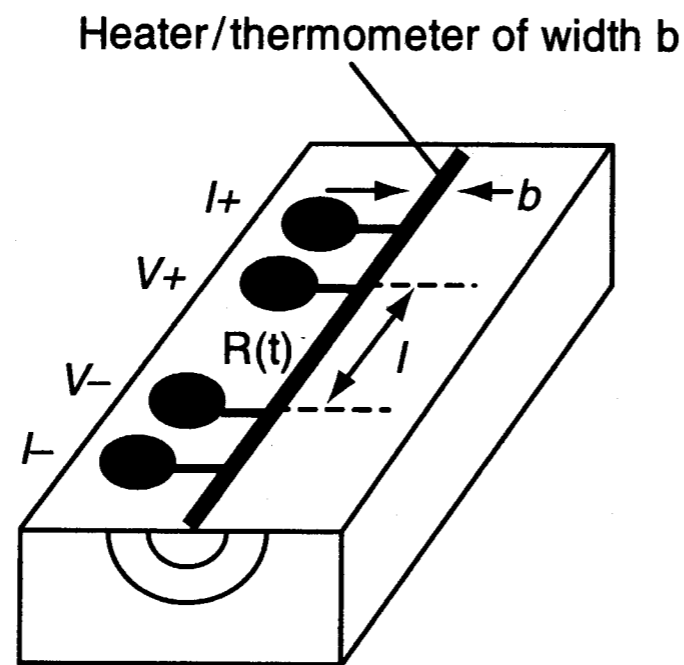
$$V = IR \sim 3\omega$$

- AC current of frequency  $\omega$  will produce Joule heating =  $I^2R$  at frequency  $2\omega$
- Measured voltage,  $V = IR$  will have both an  $\omega$  and  $3\omega$  component
- $V = IR = I_0 e^{i\omega t} \left[ R_0 + \frac{\delta R}{\delta T} \Delta T \right]$

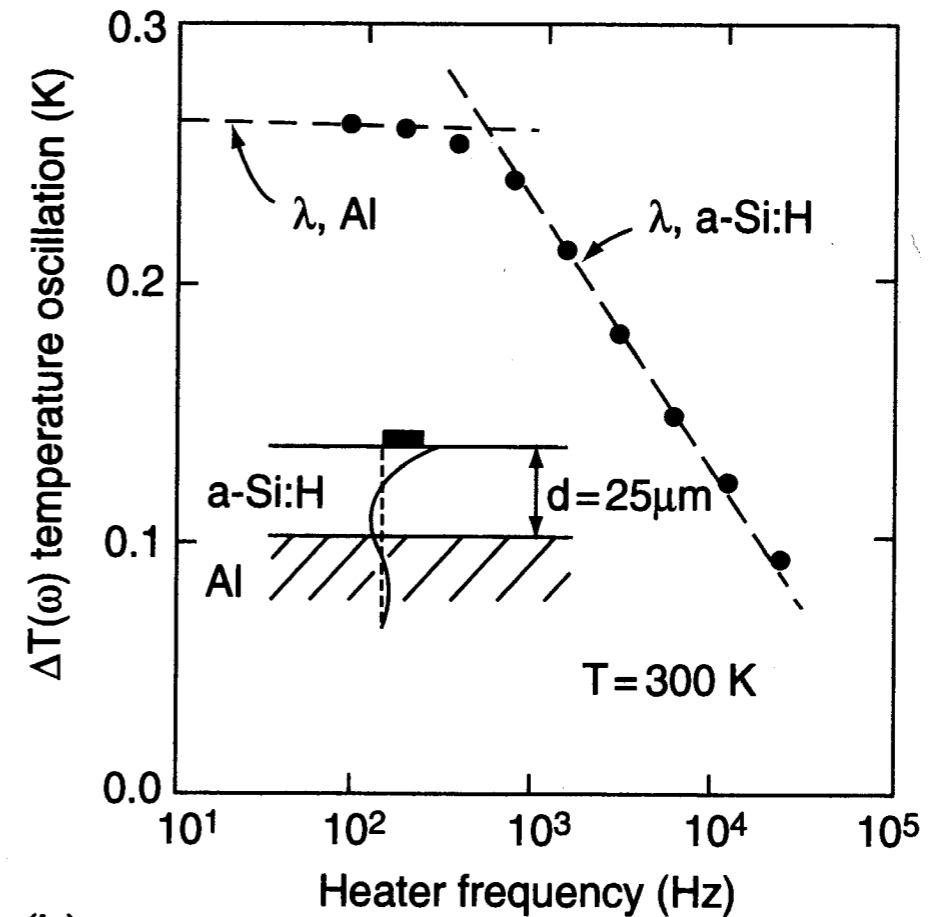
$$V = I_0 e^{i\omega t} (R_0 + C_0 e^{i2\omega t})$$

# 3 $\omega$ Technique for Measuring Thermal Conductivity

V applied at frequency  $\omega$



(a)

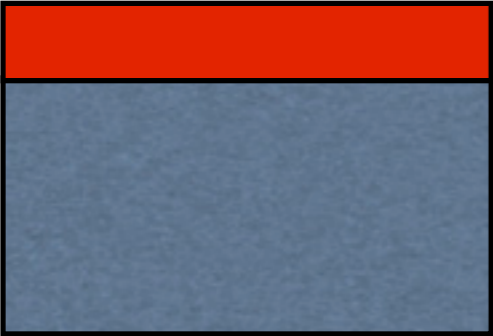


(b)

$$\kappa = \frac{V^3 \ln\left(\frac{\omega_1}{\omega_2}\right)}{4\pi I R^2 [V_3(\omega_2) - V_3(\omega_1)]} \frac{dR}{dT}$$

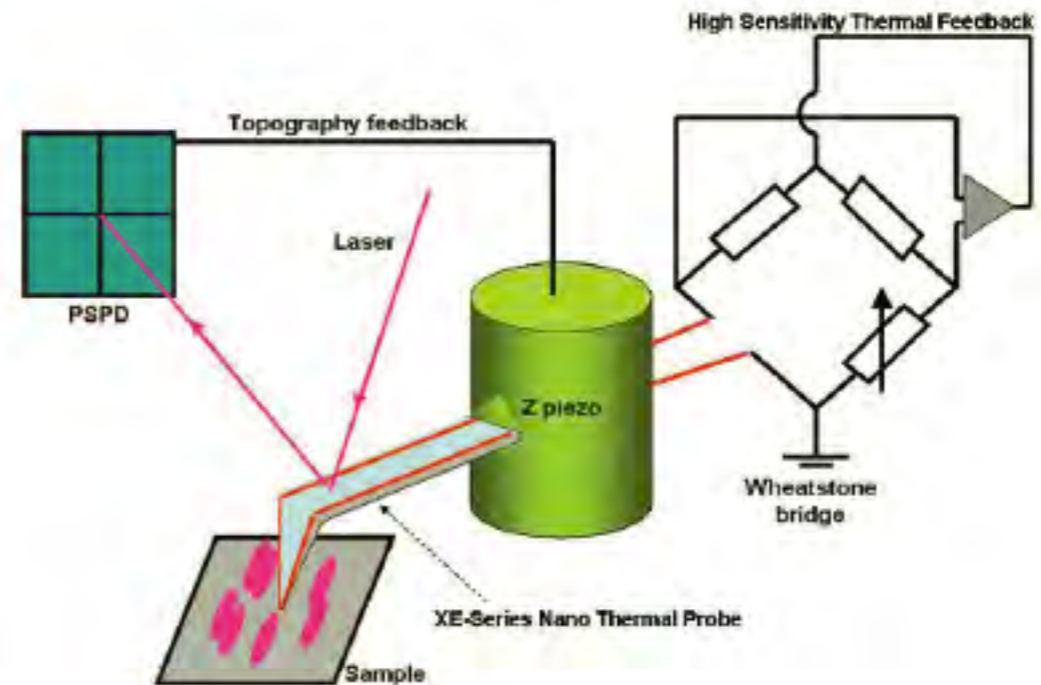
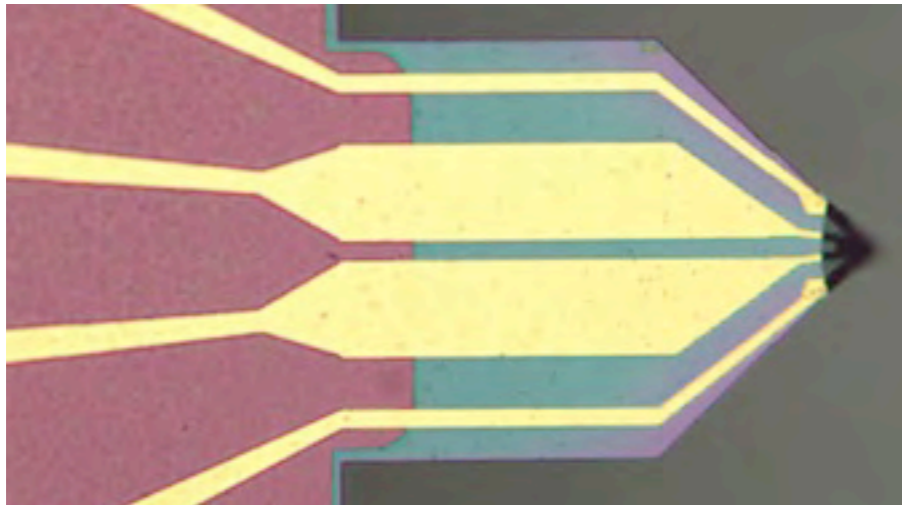
●  $V_3(\omega_1)$  and  $V_3(\omega_2)$  are voltages at 3<sup>rd</sup> harmonic frequencies  $\omega_1$  and  $\omega_2$

# 3 $\omega$ Issues and Limitations

- 3 $\omega$  technique uses 1<sup>st</sup> term from Taylor expansion i.e. approximation
- 3 $\omega$  technique only works for uniform bulk layers A diagram showing a rectangular cross-section of a material. The top portion is a thin red layer, and the bottom portion is a thicker blue layer. This represents a uniform bulk layer structure.
- Superlattices and quantum dots are seldom valid in the approximation
- Other techniques required for accurate thermal conductivity measurements

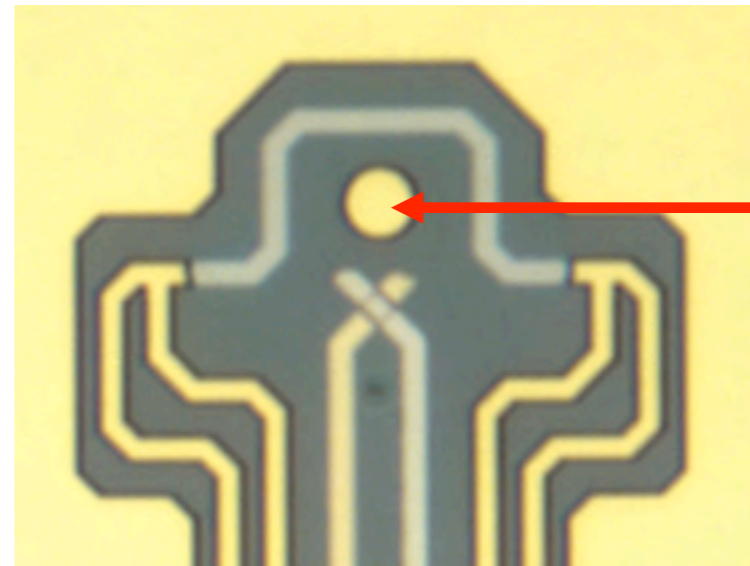
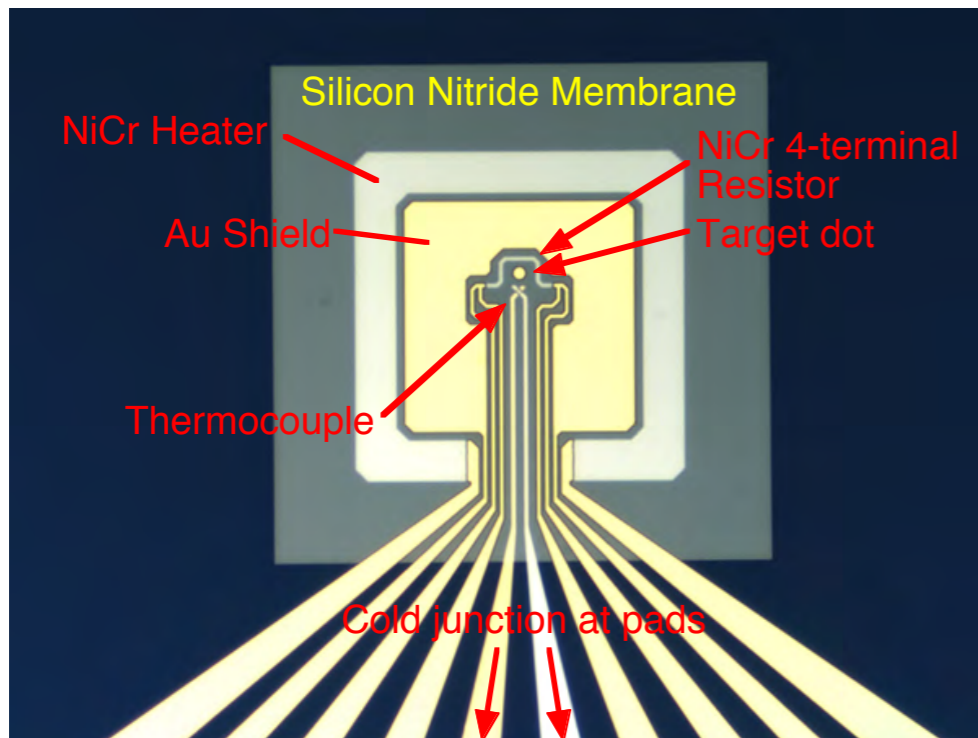


# Thermal Conductivity using Thermal AFM

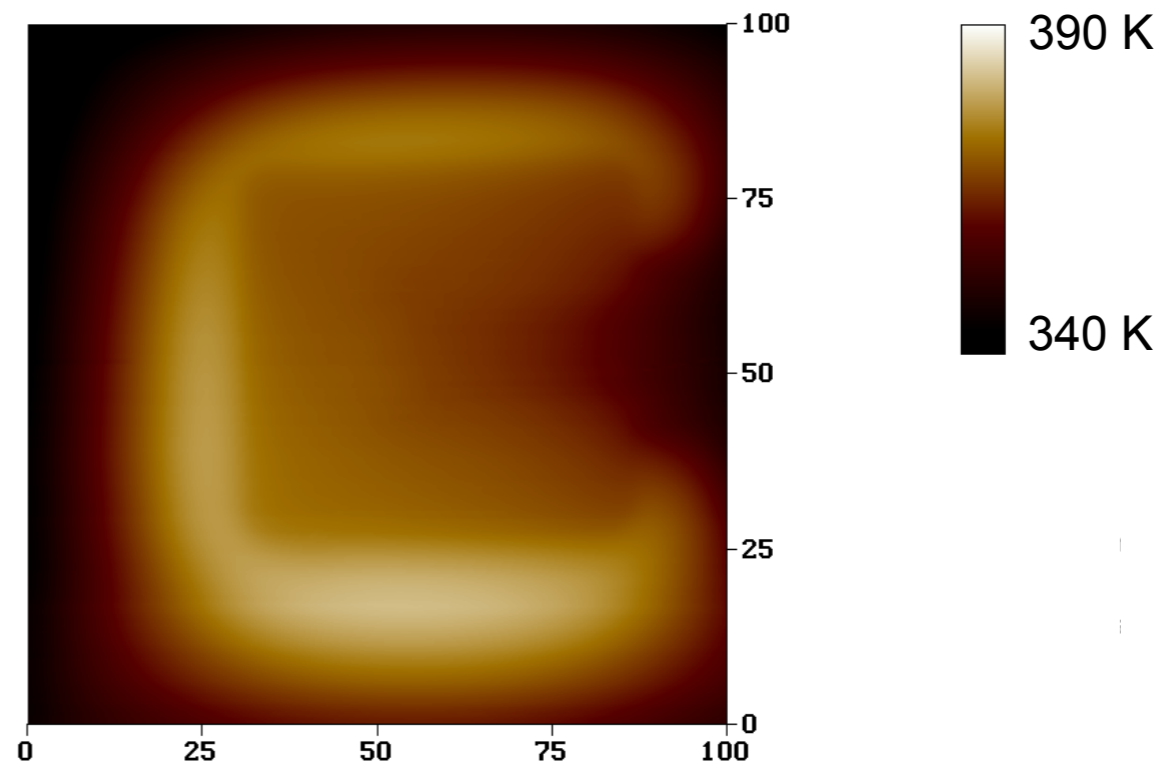
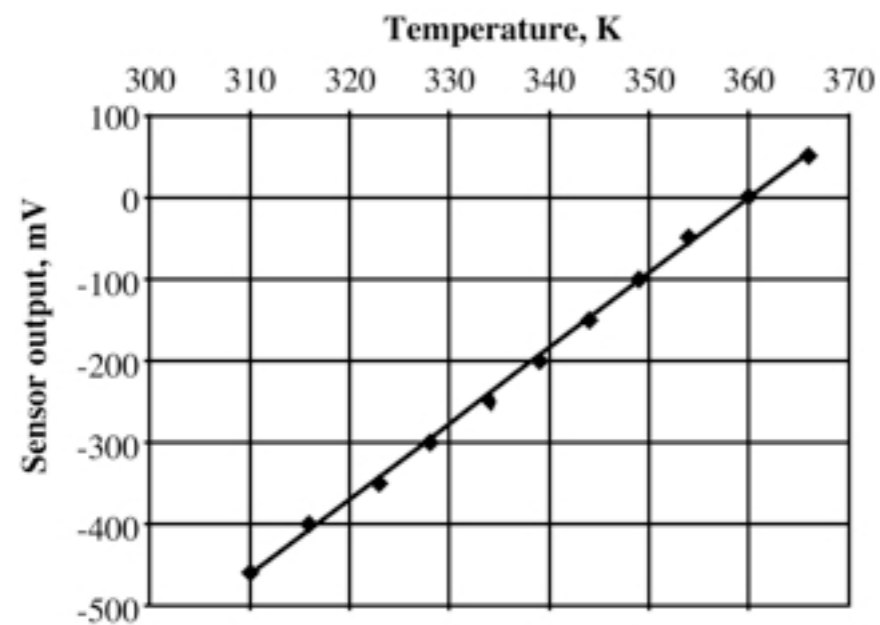


- Spatial resolution  $< 100$  nm (ideal for micro and nano structures)
- Temperature resolution to 0.1 K
- Direct temperature measurements and  $3\omega$

# Thermal Calibration

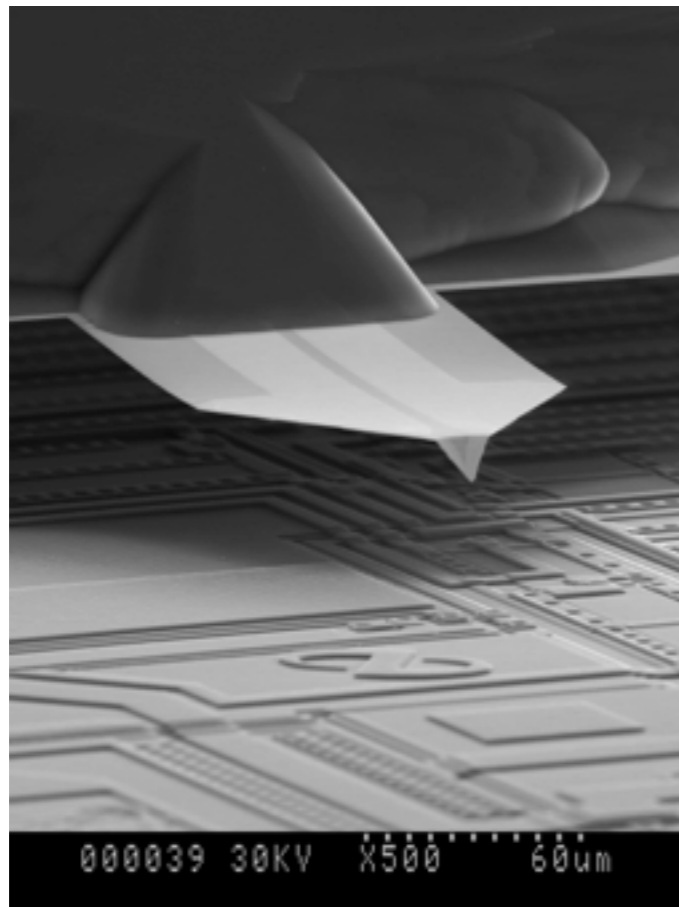


**Electrically isolated Au spot: isothermal with resistor**



*P. S. Dobson, et al., Rev. Sci. Inst. 76, 054901 (2006)*

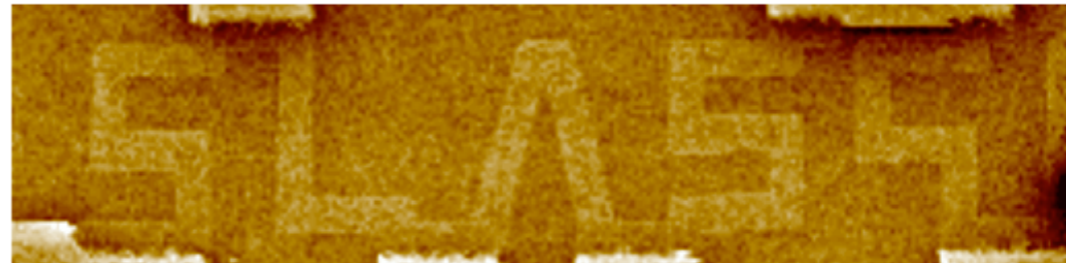
# AFM Thermal Measurements



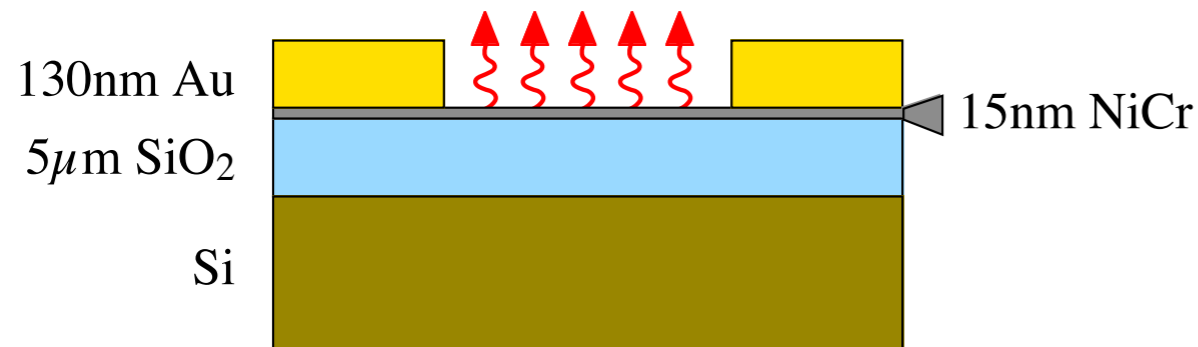
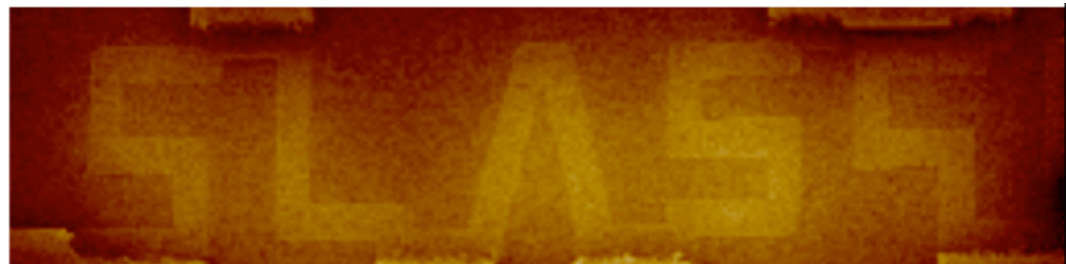
Topography



Thermal  
conduction



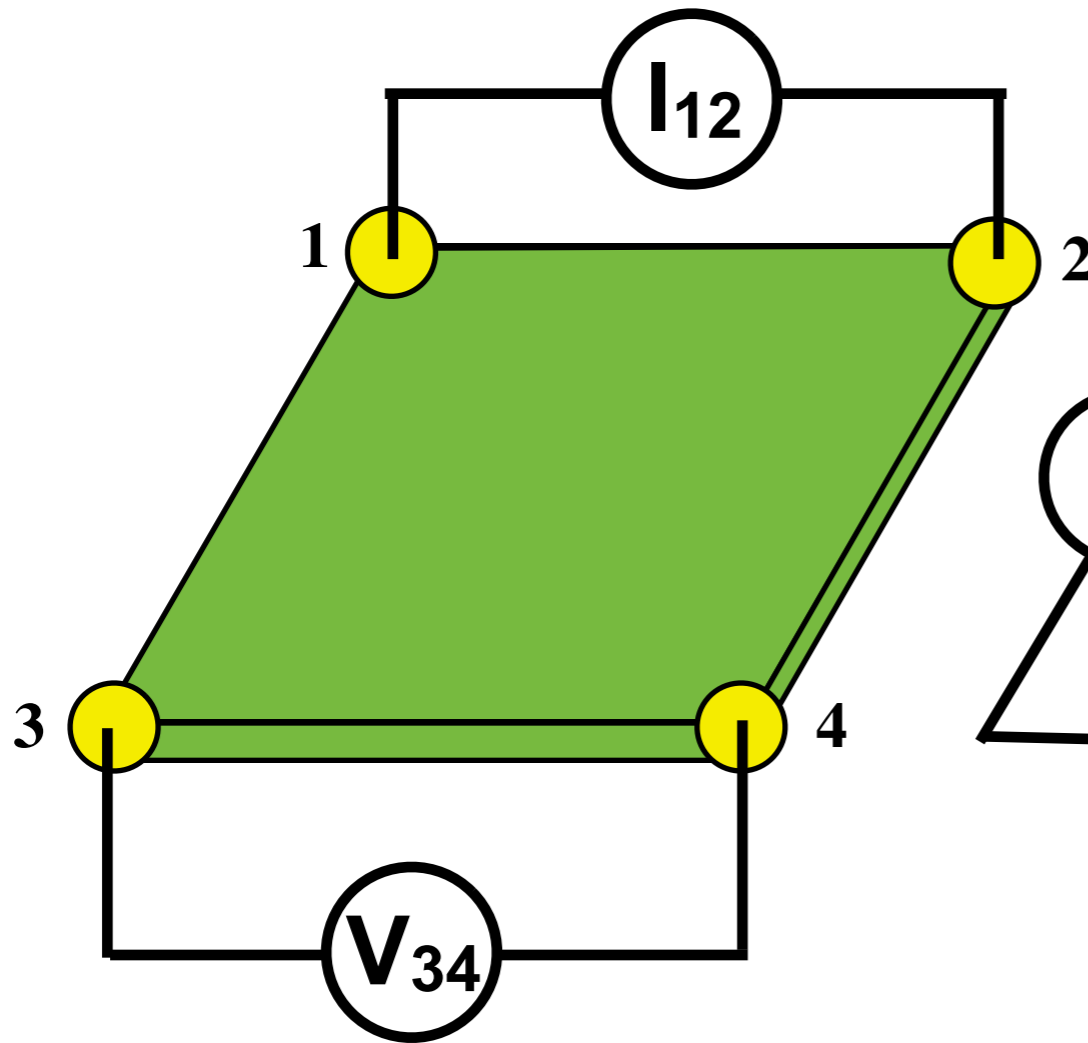
Temperature



Lock in signal 35 kHz  $2\omega$

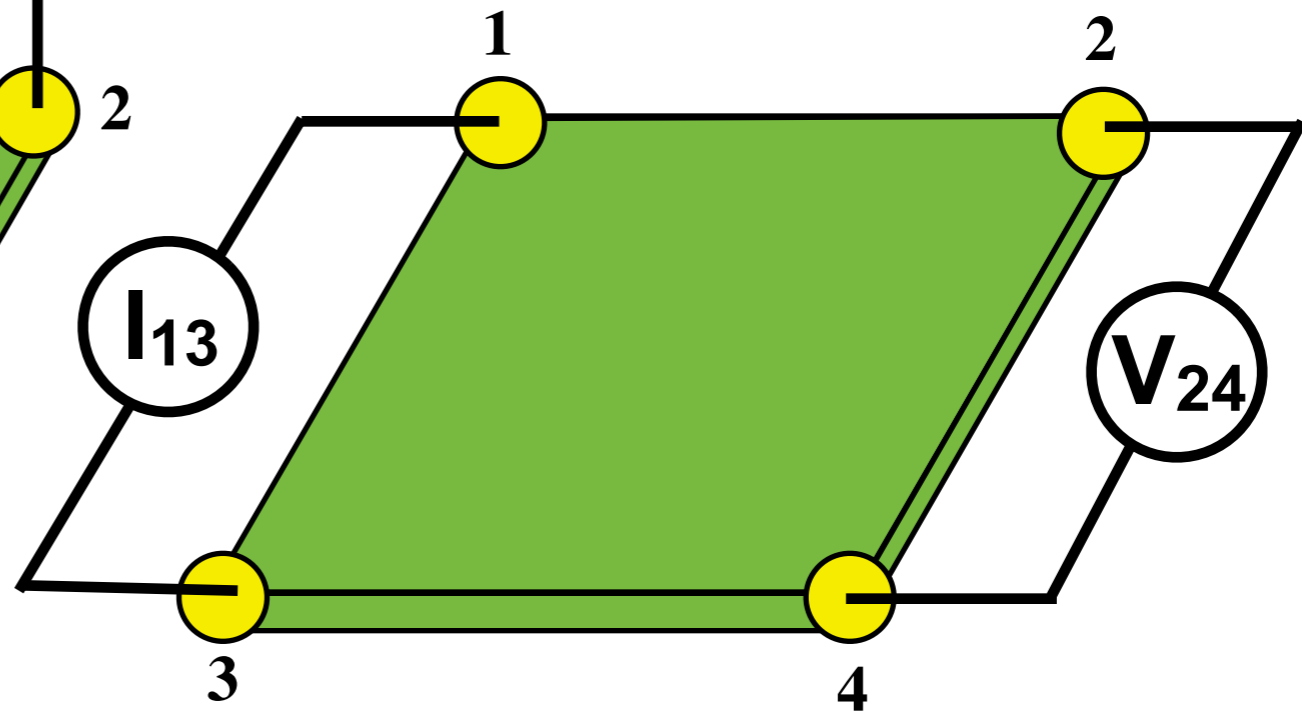
*P.D. Dobson, J.M.R. Weaver et al.*

# Electrical Measurements: Van der Pauw



For a square

$$\sigma = \frac{I_{12}}{V_{34}} = \frac{I_{13}}{V_{24}}$$



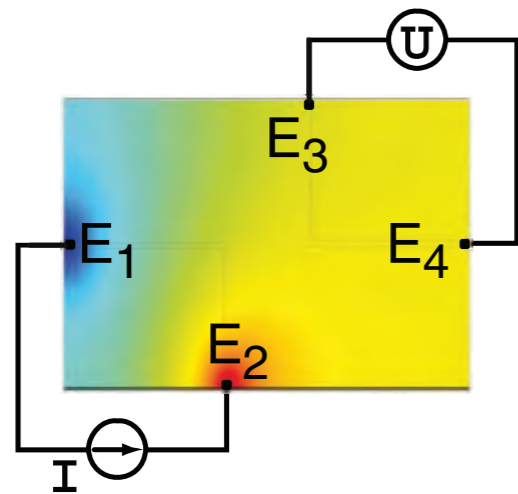
If contact area large then  $\Delta\sigma > 50\%$

$\Delta\sigma$  increases for smaller devices  
and larger contacts

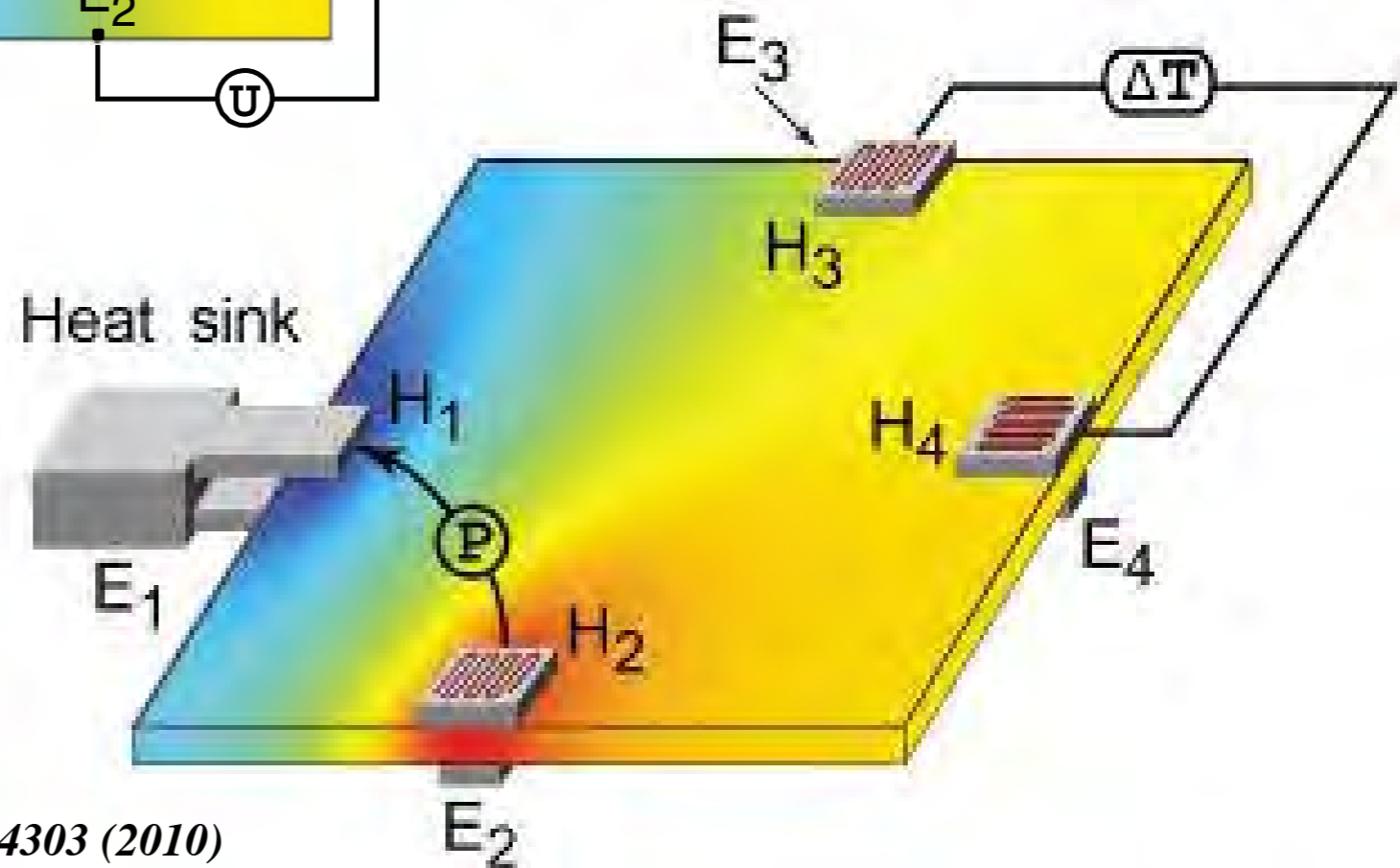
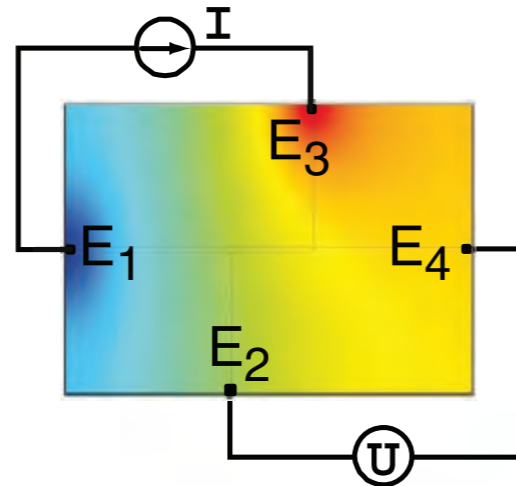
# Combined $\sigma$ and $\kappa$ from van der Pauw

a)

electrical characterization

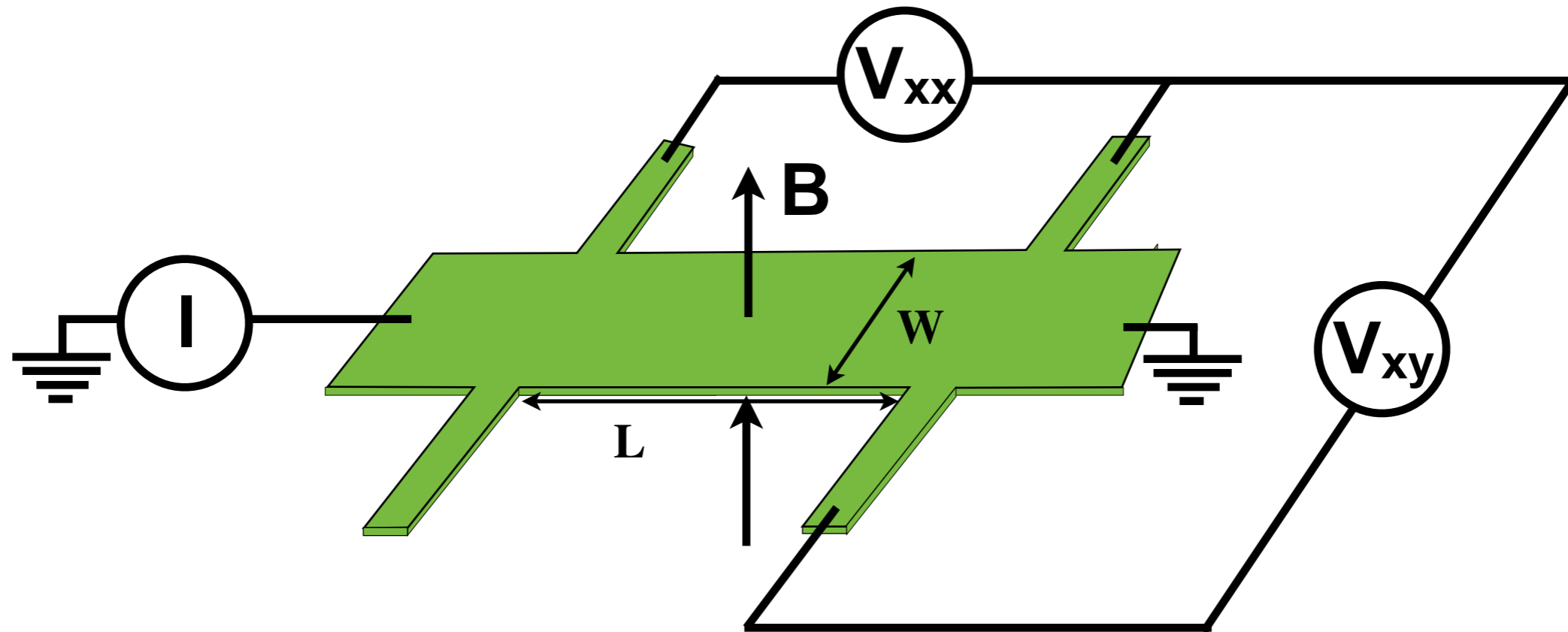


b)



*J. de Boor and V. Schmidt, Adv. Mat. 22, 4303 (2010)*

# Electrical Measurements: Hall Measurements

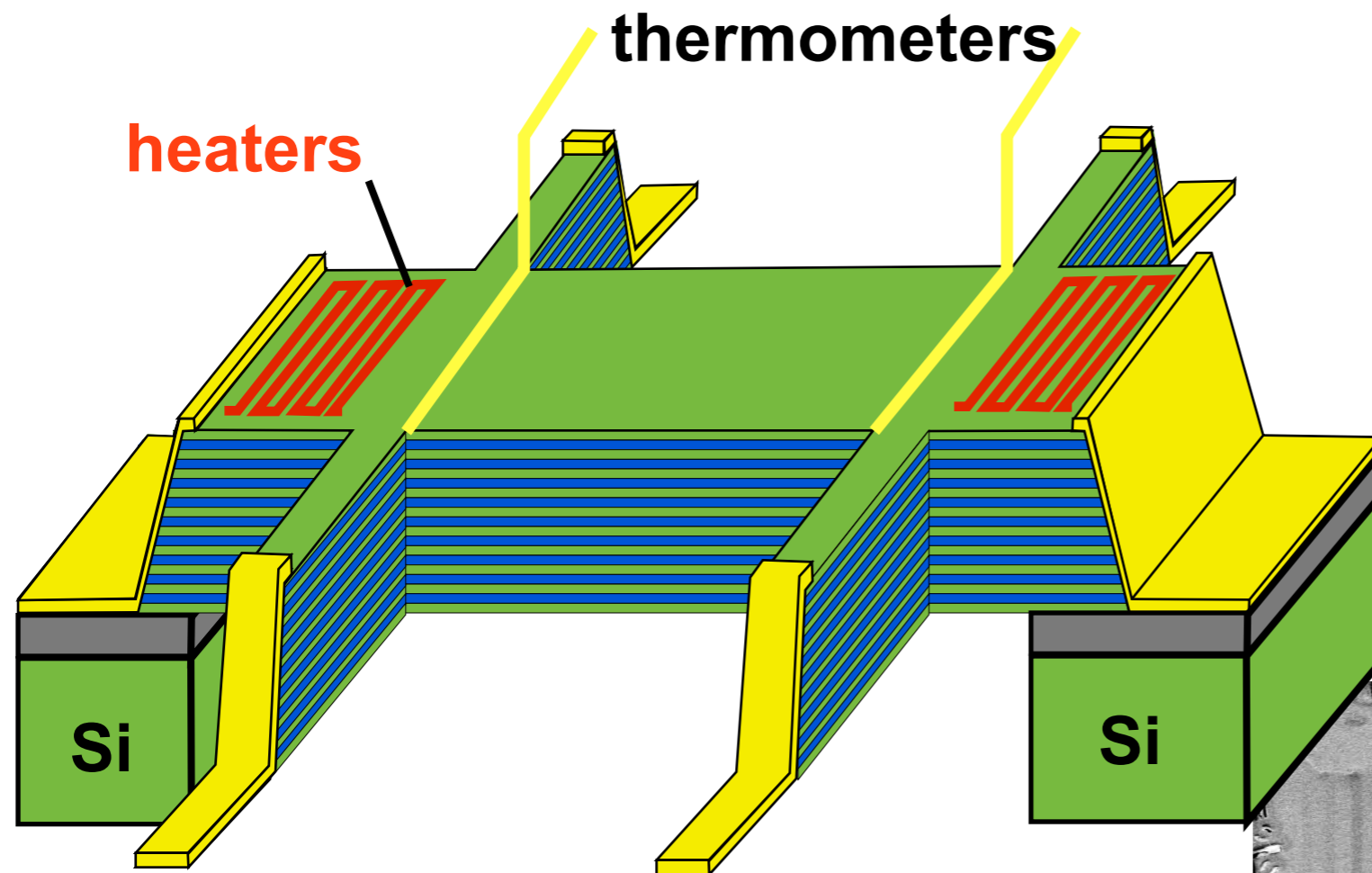


$$\sigma = \frac{IW}{V_{xx}L}$$

If  $L > 3W$  then  $\Delta\sigma < 10^{-3}$

Application of magnetic field,  $B$  gives carrier density and mobility through  $V_{xy}$  measurement

# $\alpha$ , $\kappa$ , $\sigma$ and ZT Measurements in Single Device



# The Uncertainty in Measuring ZT

- Many materials with  $ZT > 1.5$  reported but few confirmed by others
- No devices demonstrated with such high efficiencies
- Due to: measurement uncertainty & complexity of fabricating devices

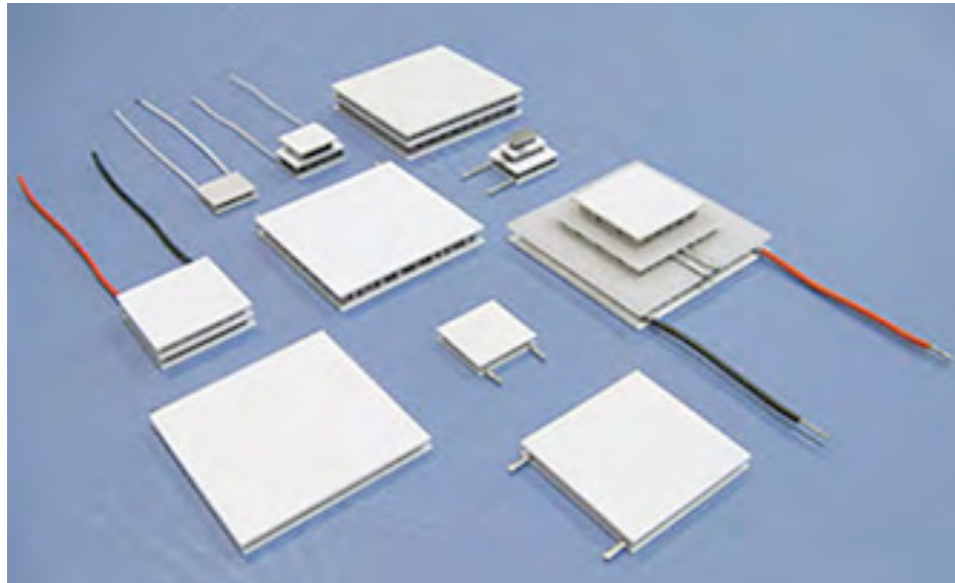
- $$\frac{\Delta(ZT)}{ZT} = 2 \frac{\Delta\alpha}{\alpha} + \frac{\Delta\sigma}{\sigma} + \frac{\Delta\kappa}{\kappa} + \frac{\Delta T}{T}$$

$\Delta x$  = uncertainty in  $x$  = standard deviation in  $x$

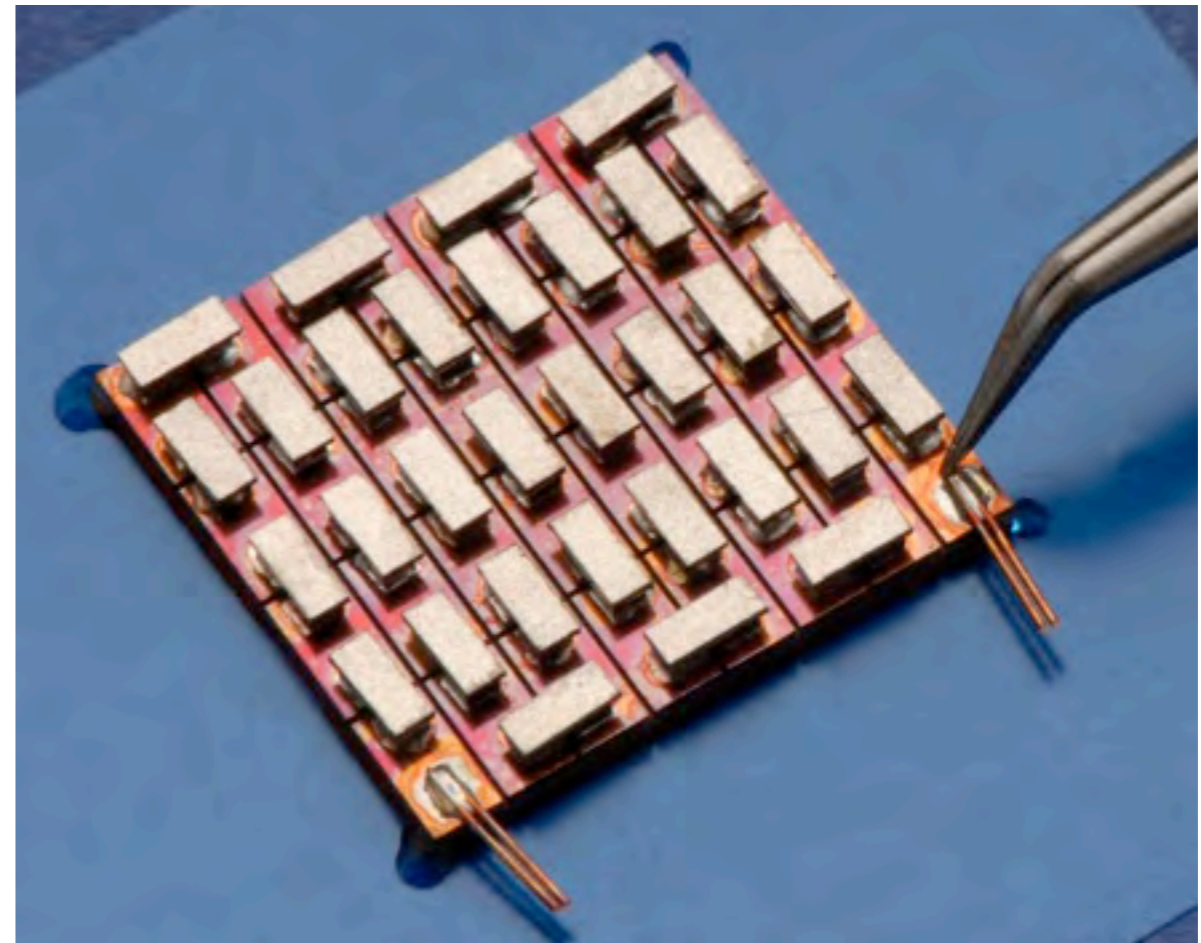
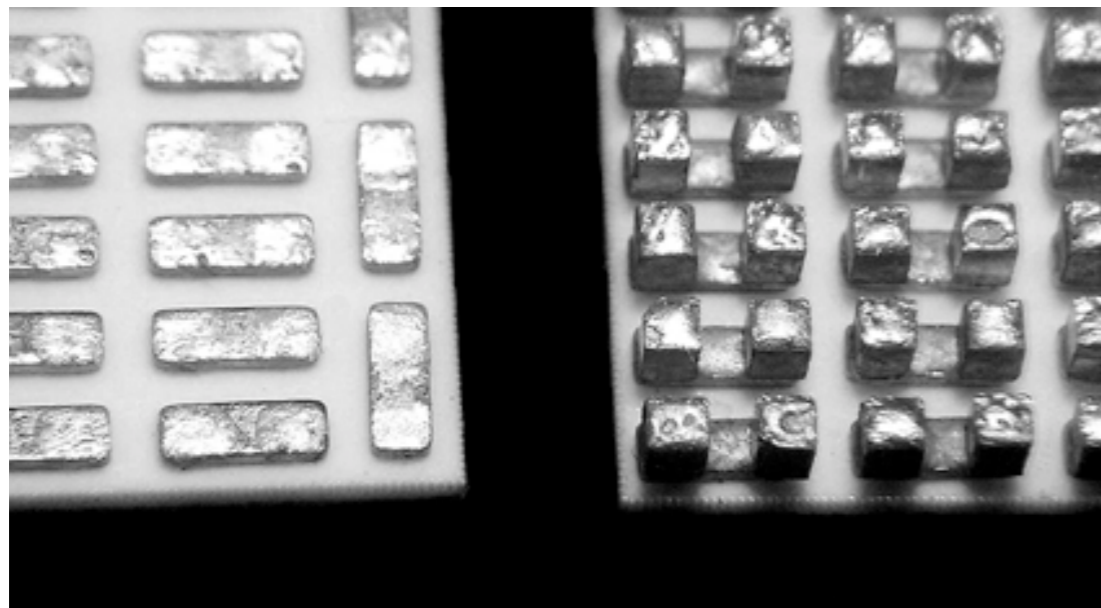
- Measurements are conceptually simple but results vary considerably due to thermal gradients in the measurements → systematic inaccuracies
- Total ZT uncertainty can be between 25% to 50%



# Thermoelectric Generators / Peltier Coolers



Bulk n-Bi<sub>2</sub>Te<sub>3</sub> and p-Sb<sub>2</sub>Te<sub>3</sub> devices

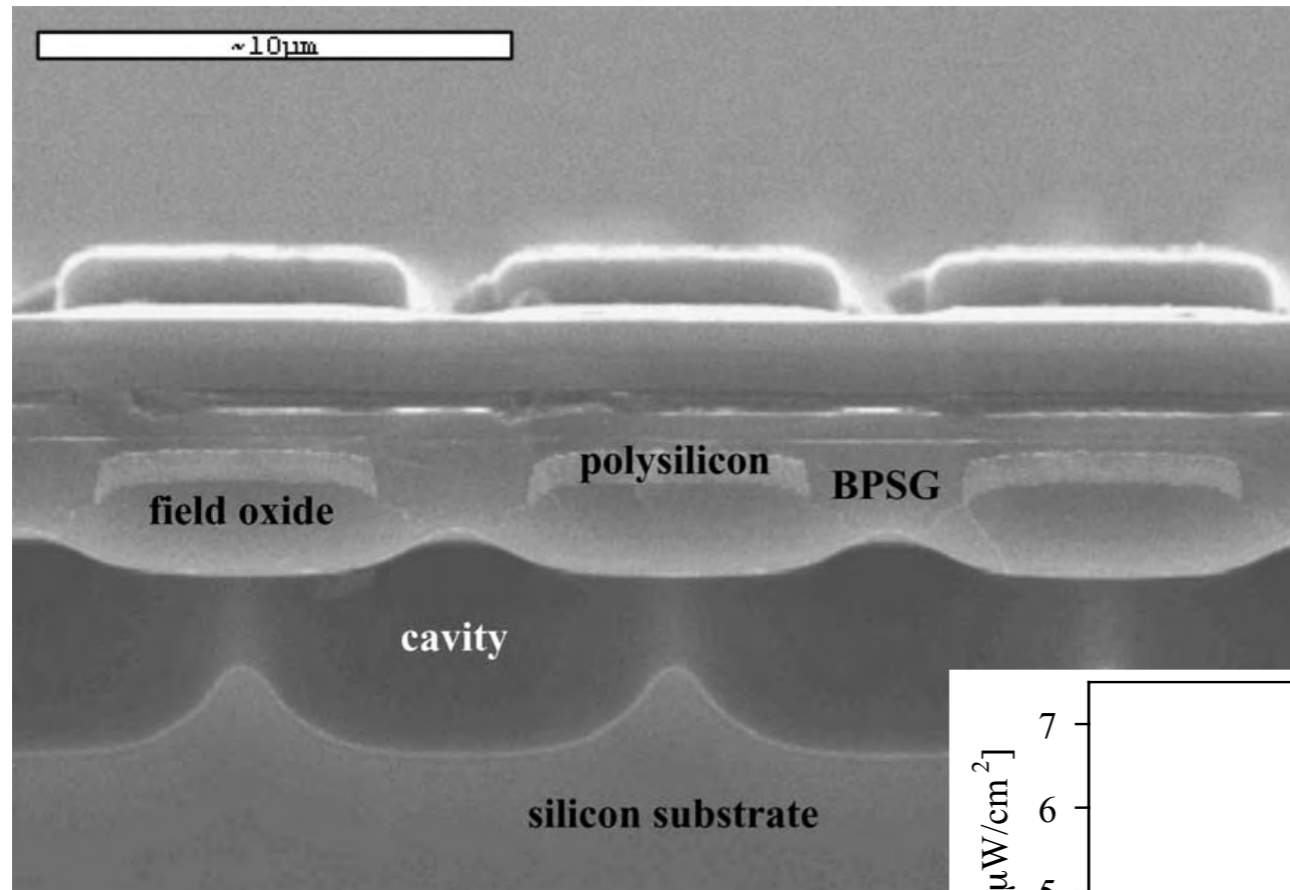


*D.J. Paul*  
*School of Engineering*



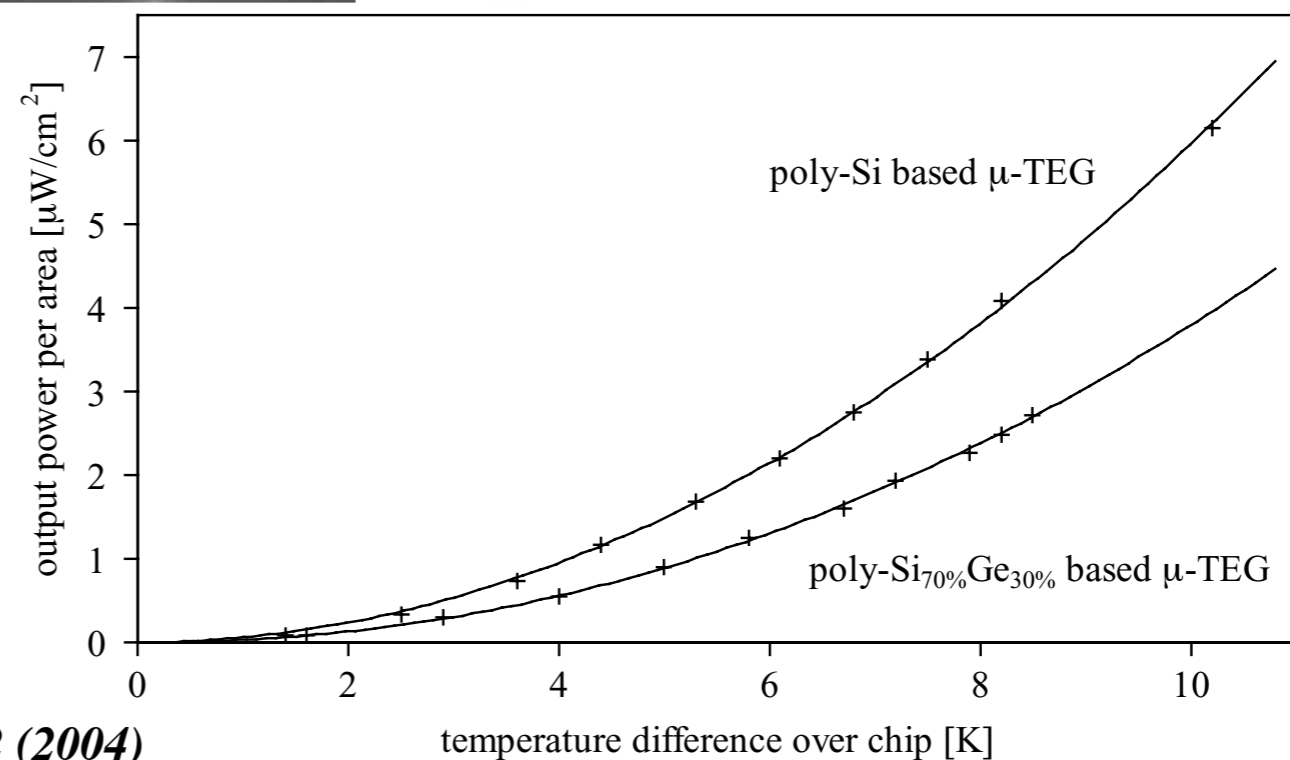
University  
of Glasgow

# Small Scale Microfabricated Energy Harvesting



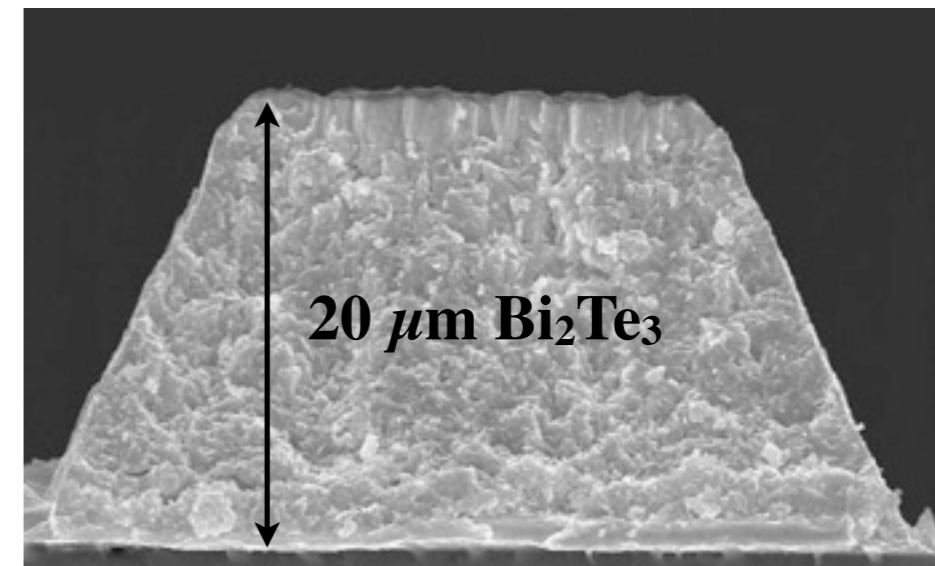
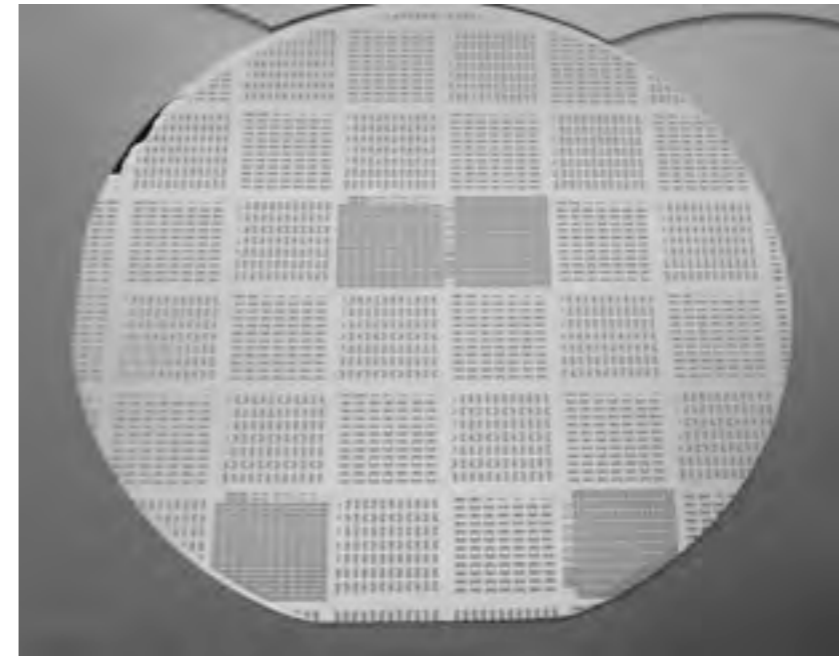
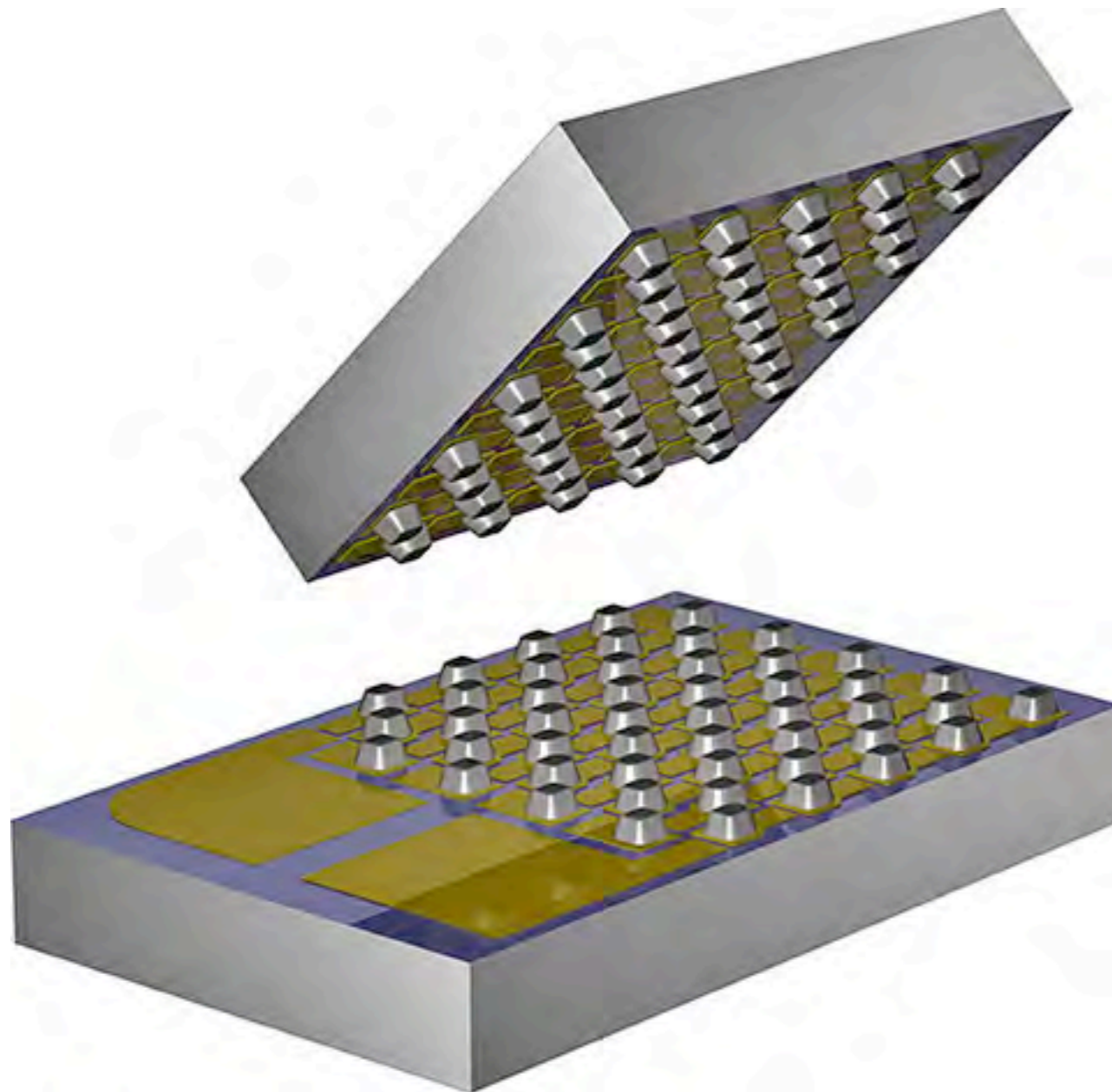
- Si process: poly-Si
- $\alpha_{n+p} = 160 \mu\text{V/K}$
- $\kappa = 31.4 \text{ Wm}^{-1}\text{K}^{-1}$
- $\rho = 1.5 \text{ m}\Omega\text{-cm}$

$\Delta T = 5 \text{ K} \rightarrow 5 \text{ V}$  and  $1 \mu\text{W}$



*M. Strasser et al., Sensors Actuators A 114, 362 (2004)*

# Micropelt: Microfabricated $\text{Bi}_2\text{Te}_3$ Technology



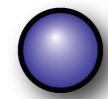
<http://www.micropelt.com/>

*D.J. Paul*  
*School of Engineering*

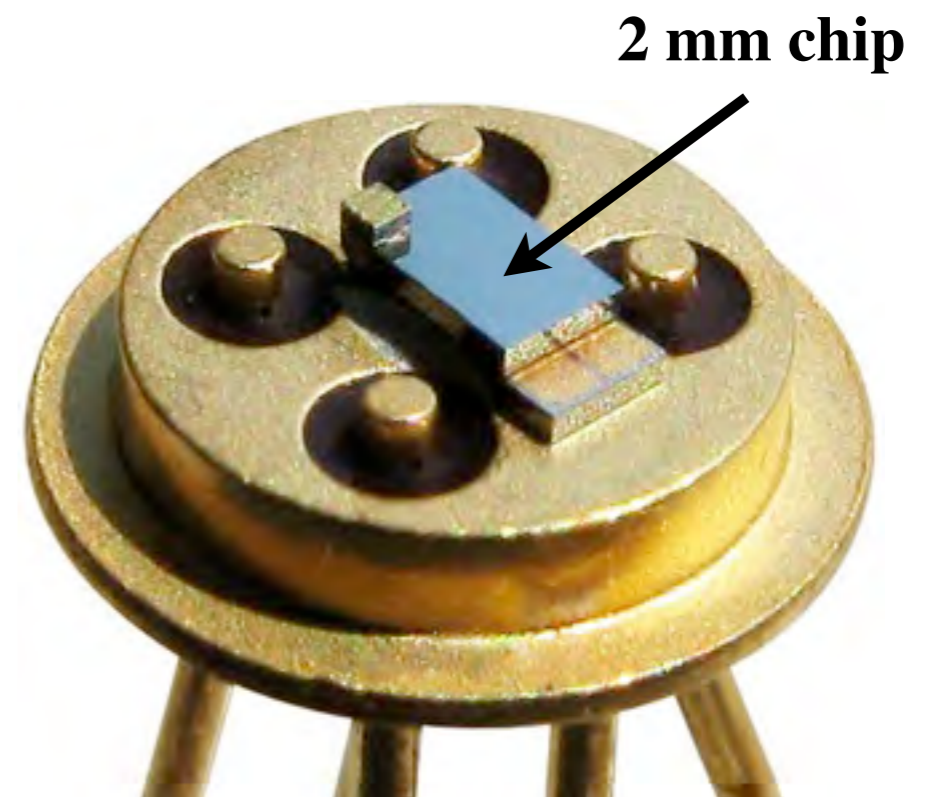
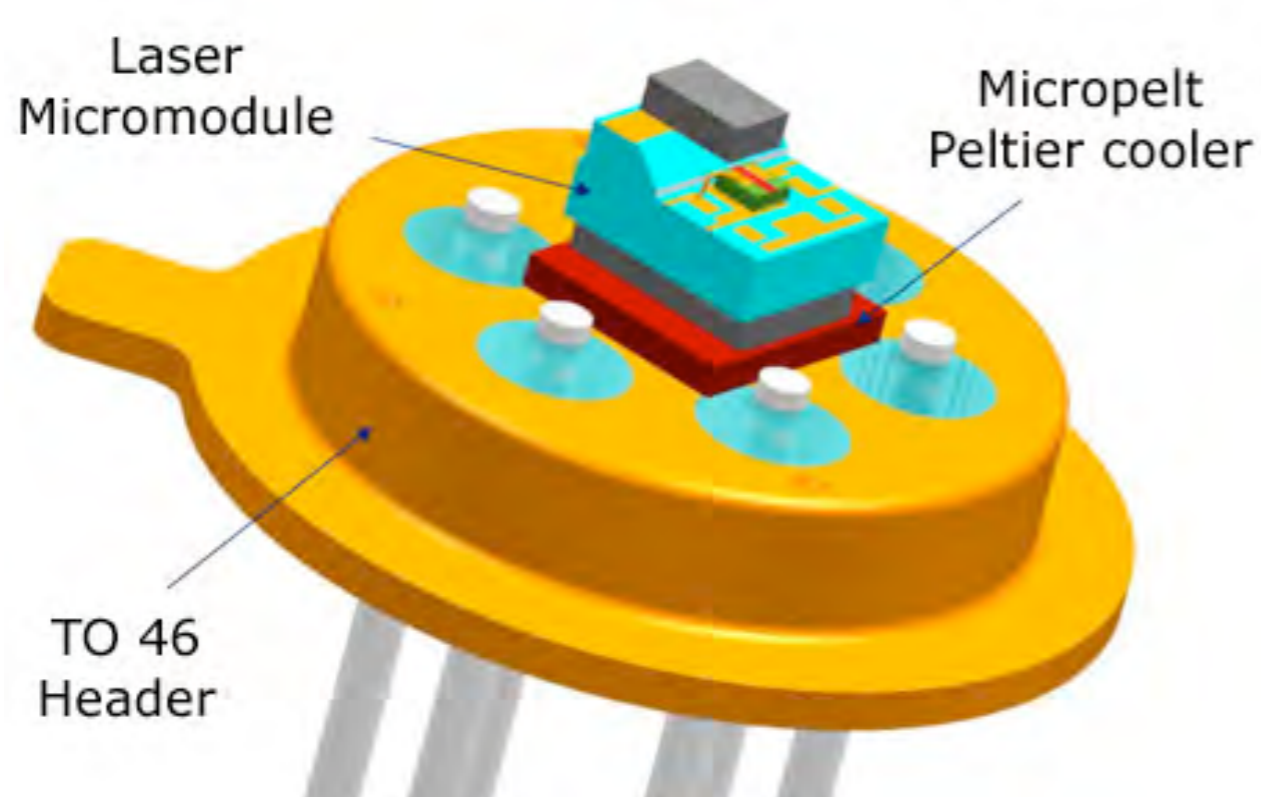


University  
of Glasgow

# Micropelt Peltier Coolers for Lasers

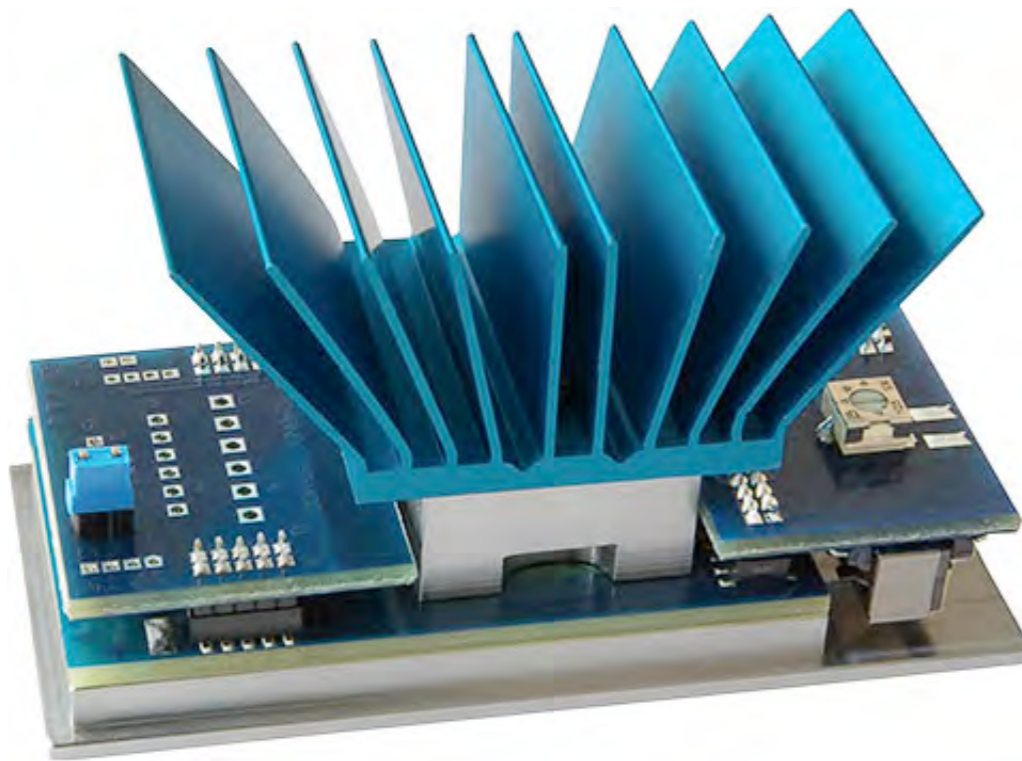


Microfabricated  $\text{Bi}_2\text{Te}_3$  thermoelectric devices

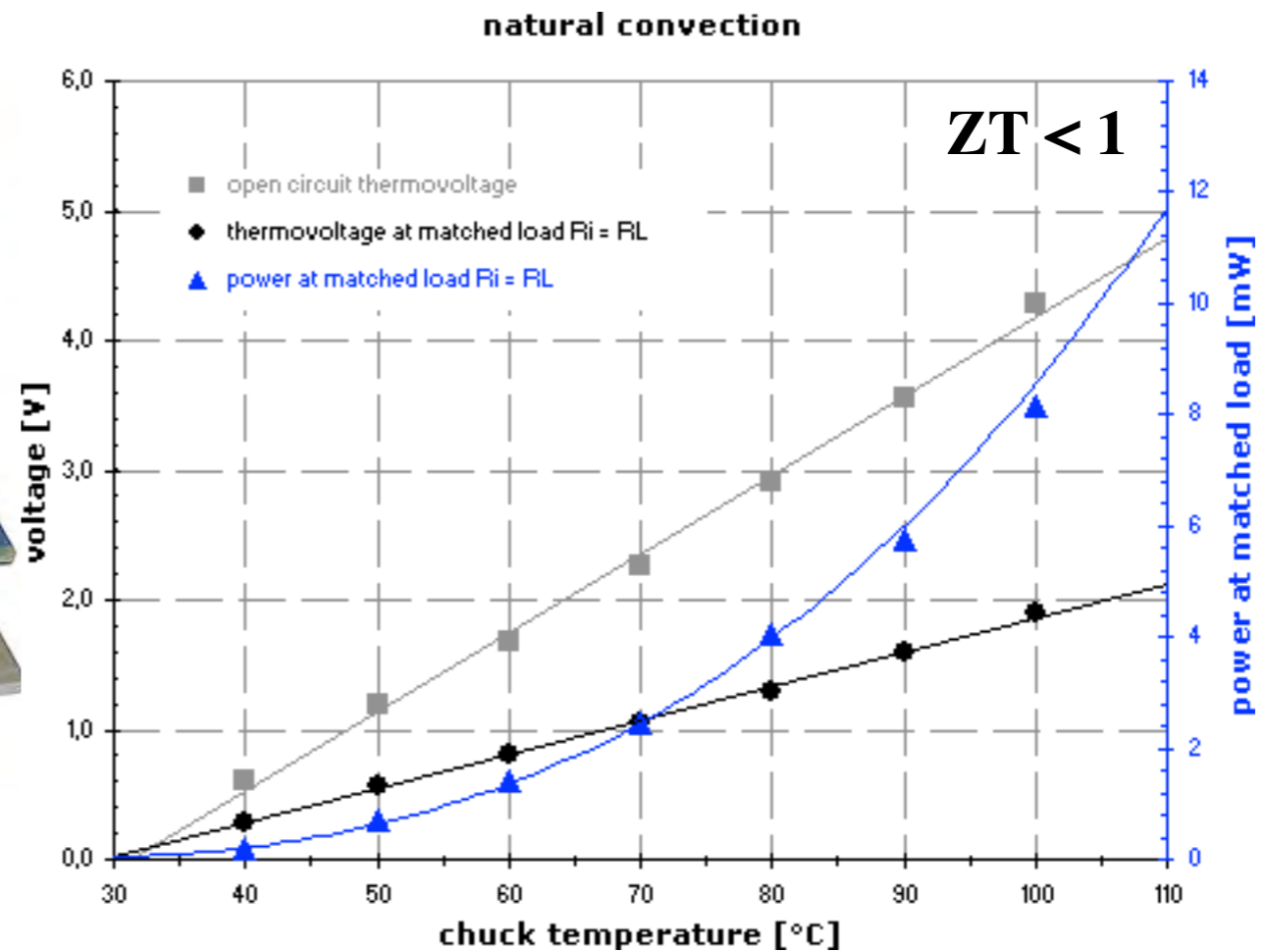


<http://www.micropelt.com/>

# Micropelt Bi<sub>2</sub>Te<sub>3</sub> Thermoelectric Energy Harvester



3.4 mm x 3.4 mm  
thermoelectric chip



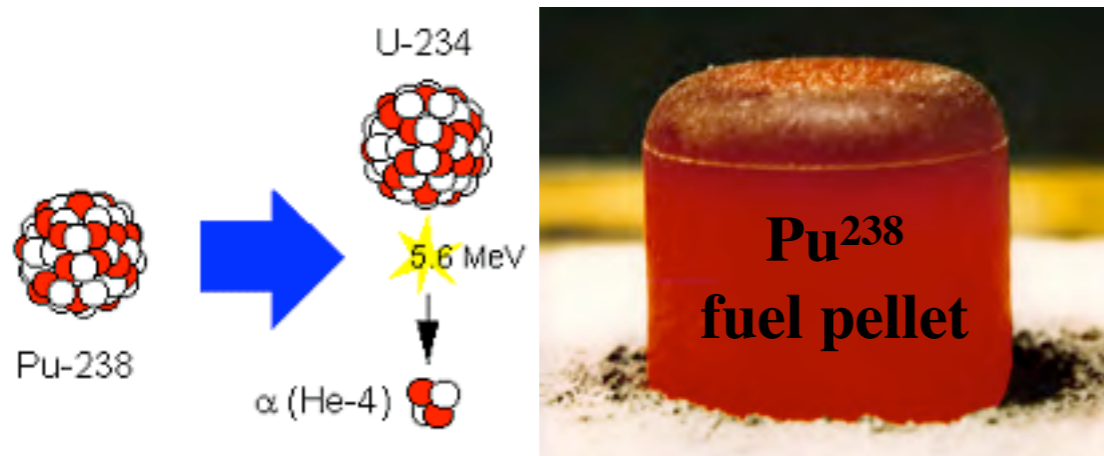
<http://www.micropelt.com/>

- **Tellurium is the 7<sup>th</sup> rarest element on planet earth**
- **Supply is limited and price fluctuations are enormous on a weekly basis**
- **Te based materials are unlikely to be available in the (near) future!**
- **Sustainable thermoelectrics needs new sustainable or plentiful materials and not  $\text{Bi}_2\text{Te}_3$  or  $\text{PbTe}$**

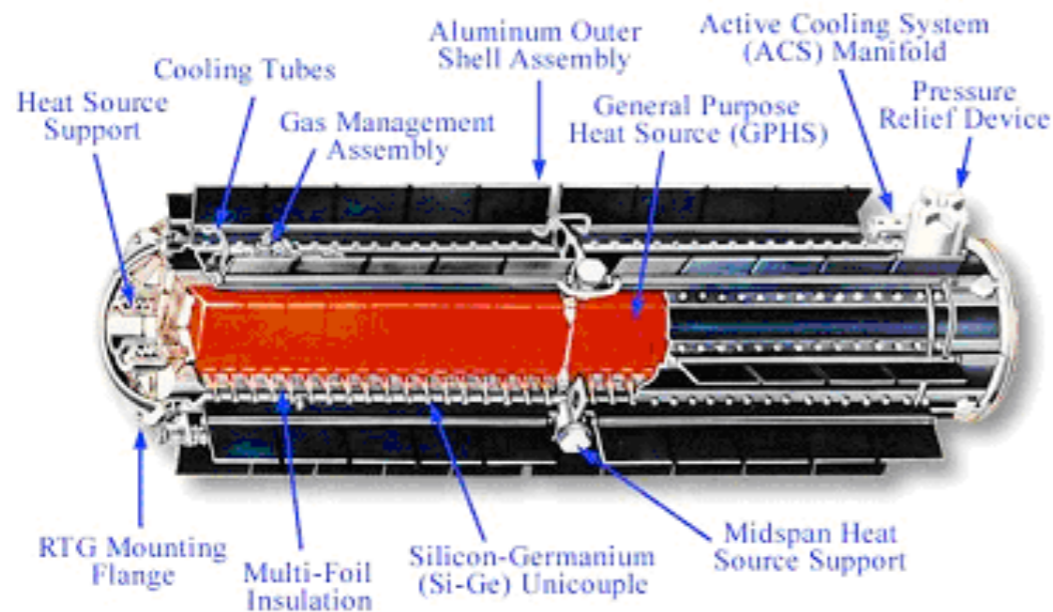


# NASA Radioisotope Thermoelectric Generator

Radioisotope heater → thermoelectric generator → electricity

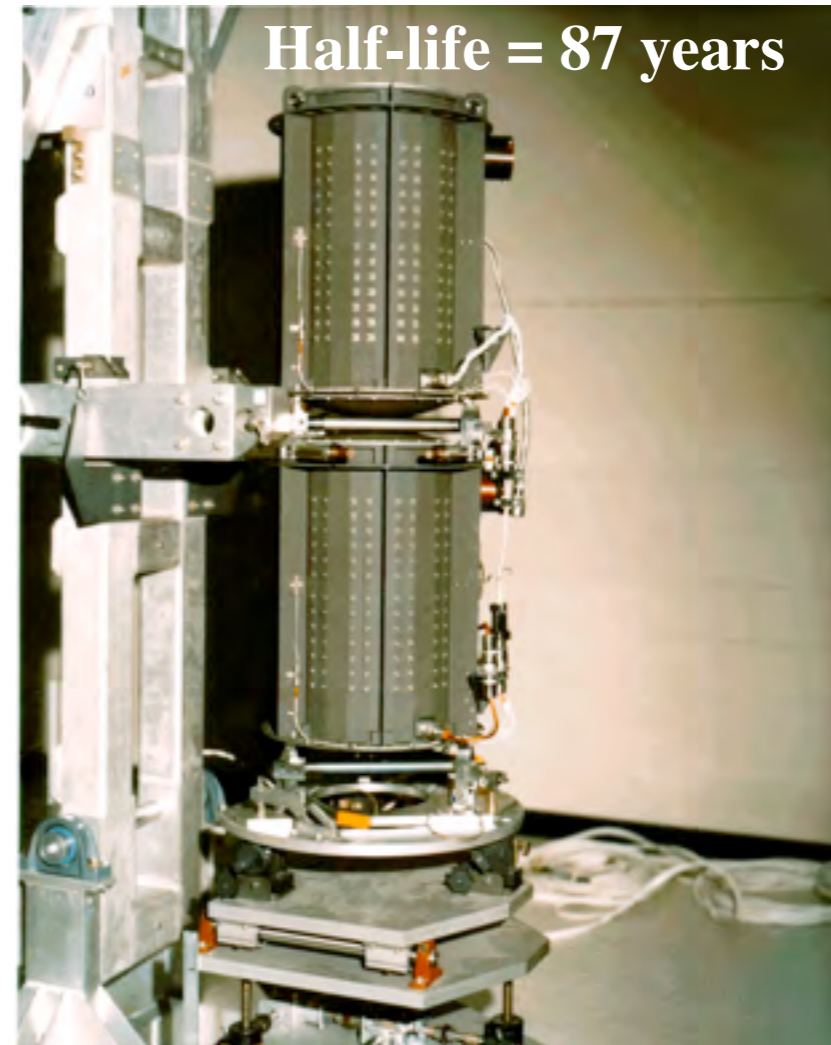


## GPHS-RTG



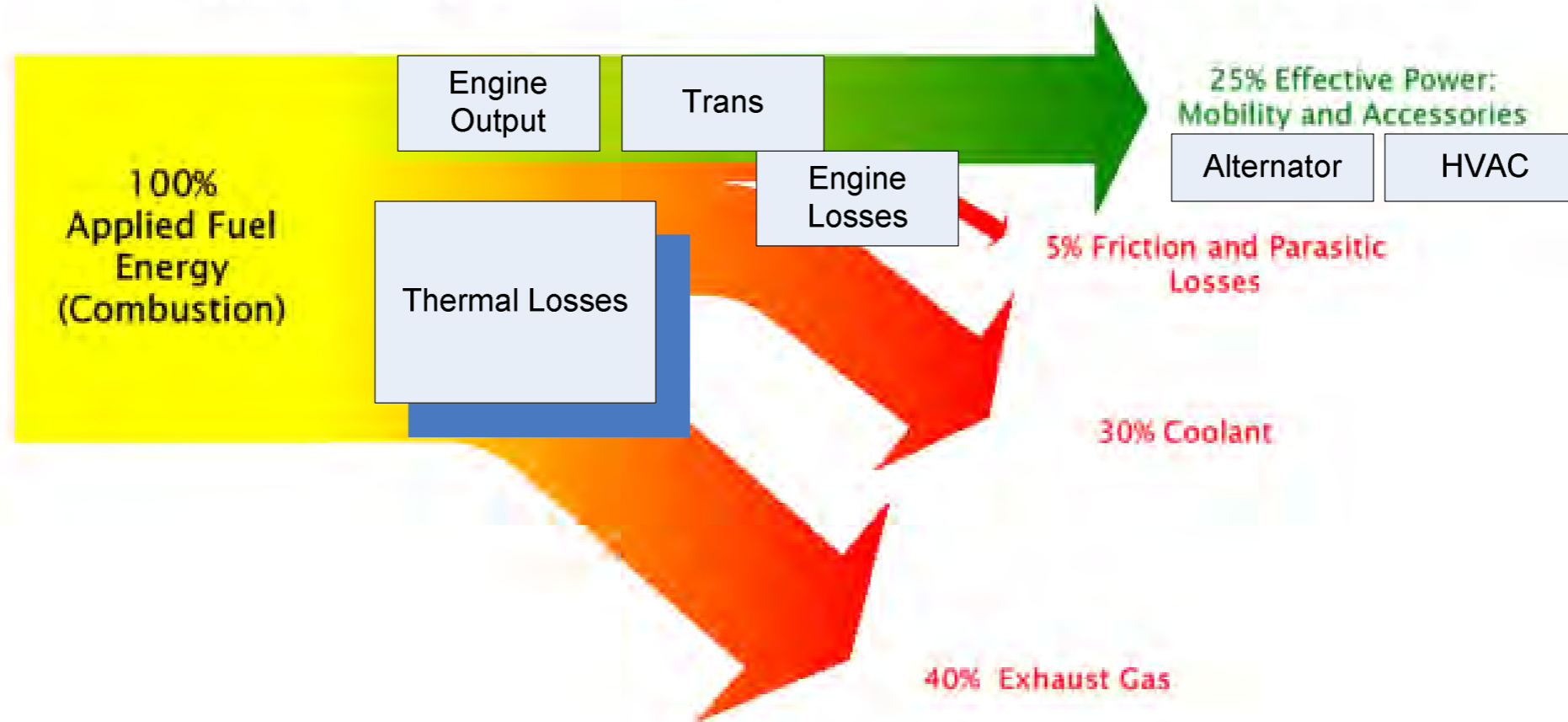
Voyager – Pu<sup>238</sup>

Half-life = 87 years



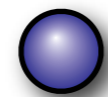
$470 \text{ W @ } 30 \text{ V on launch, after 33 years power} = 470 \times 2^{-\frac{33}{87}} = 361 \text{ W}$

# Thermoelectrics in Cars

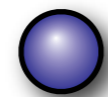


$$\text{Fuel Consumption} \propto \eta_{\text{powertrain}} \times \left( \frac{1}{2} \rho V^2 C_d A + \mu_r \times \text{mpg} \right) + \mathbf{E}_{\text{amenities}}$$

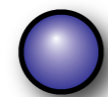
**Thermoelectrics in Cars:**



**Increase electrical supply**



**Use waste heat energy (45% of fuel!)**

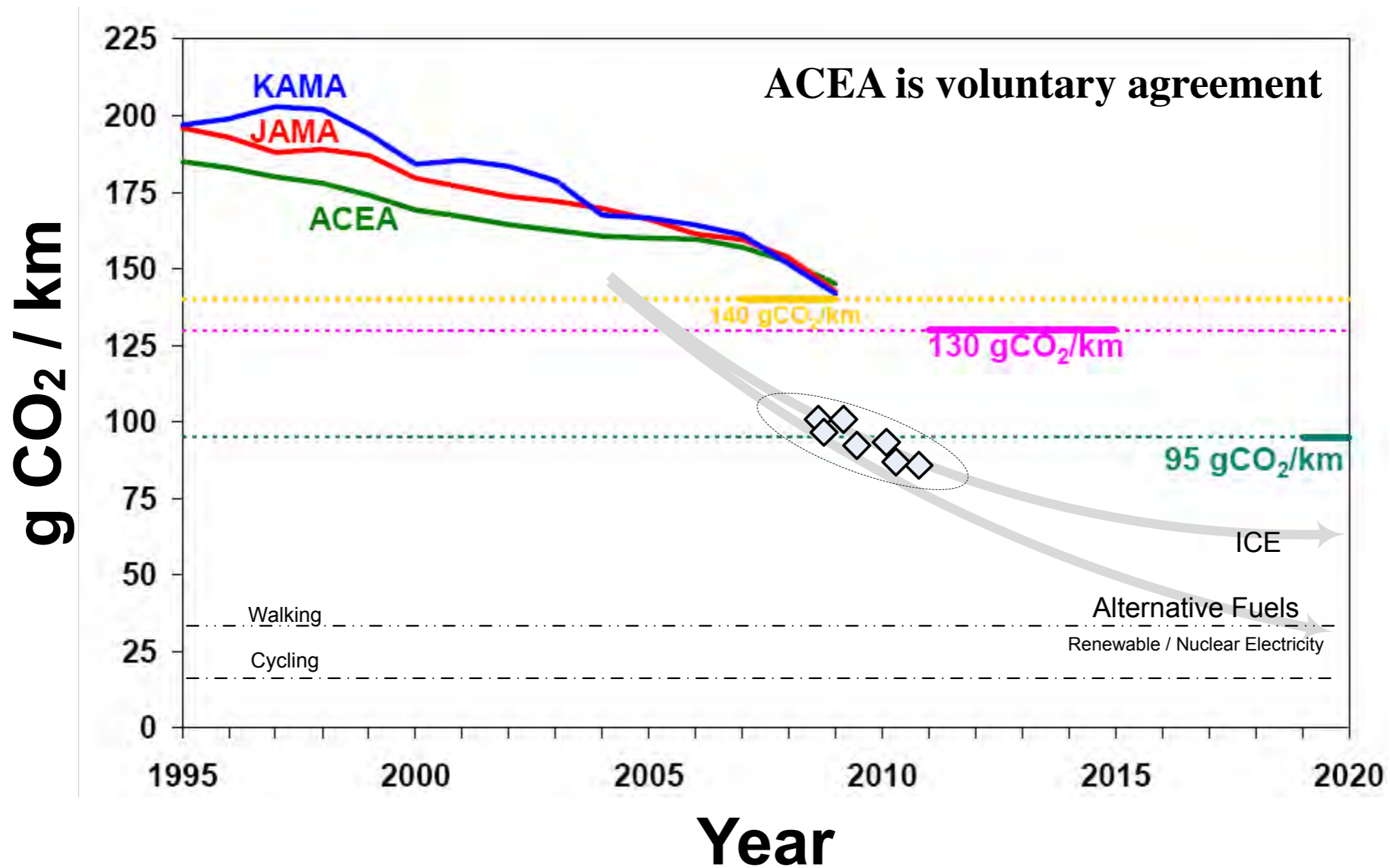


**Provide efficient local cooling**

*M. Ellis, Jaguar-Land Rover*

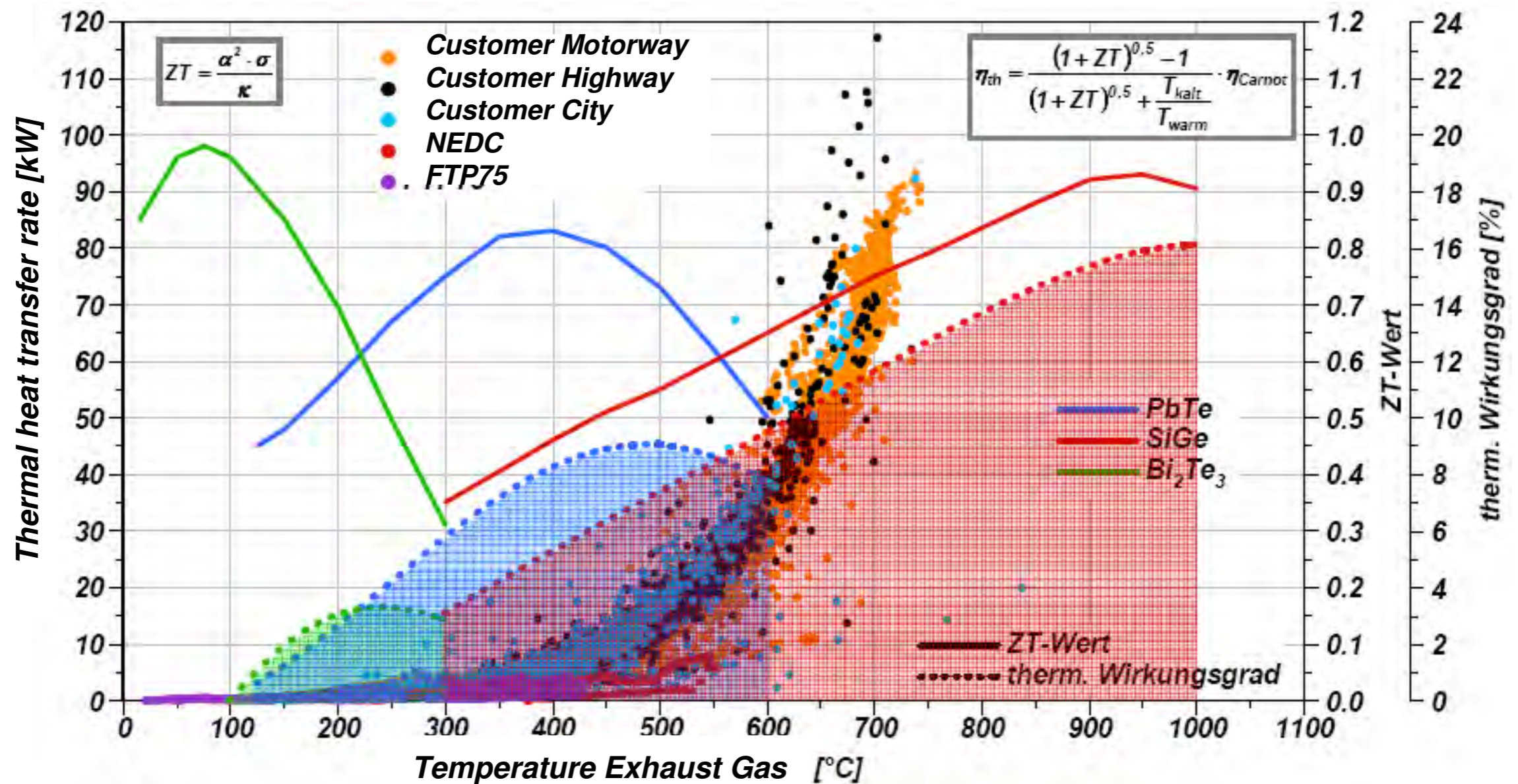


# Cars: CO<sub>2</sub> Emissions Legislation



*M. Ellis, Jaguar-Land Rover*

# Heat from Car Exhaust



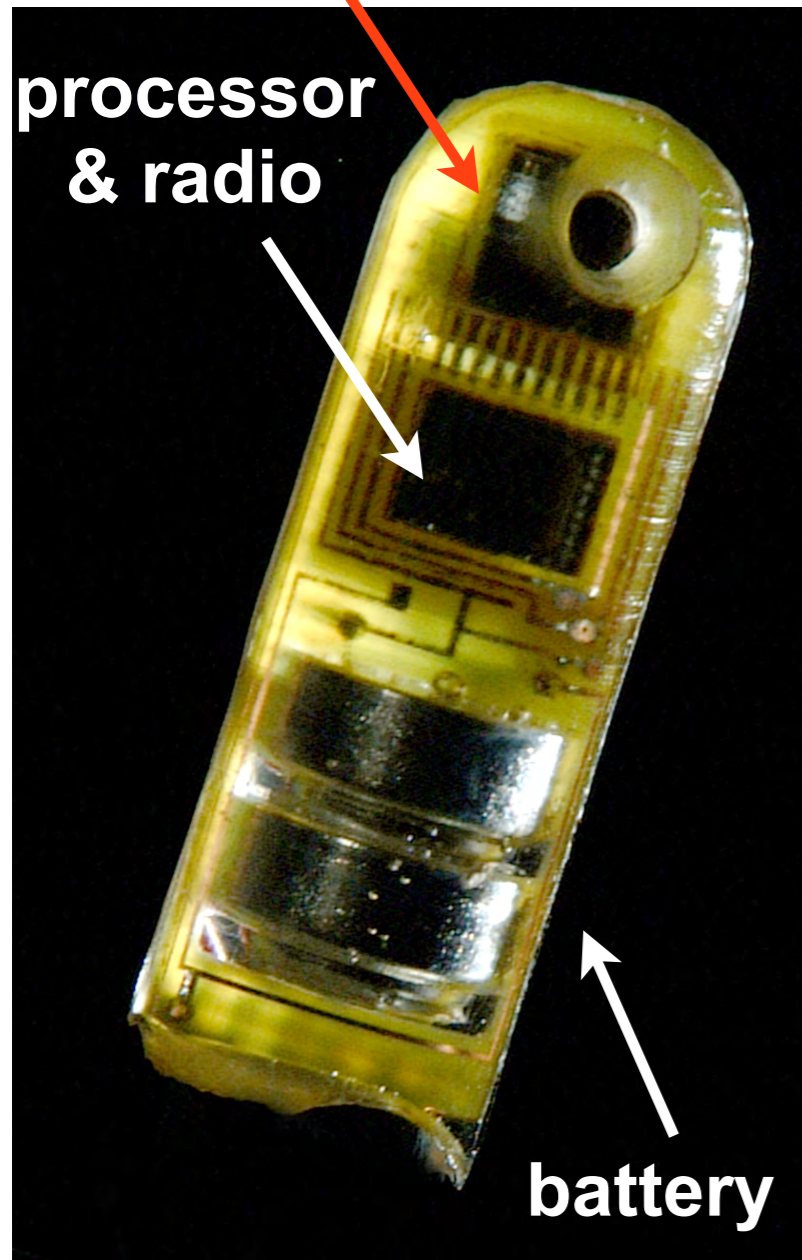
M. Ellis, Jaguar-Land Rover

# Present Thermoelectric Energy Harvesting



- **VW and BMW announced TE on exhaust in 2008: 24  $\text{Bi}_2\text{Te}_3$  modules**
- **600 W under motorway driving  $\rightarrow$   $\sim 10\%$  of car's electrical requirement**
- **5% reduction in fuel consumption through removing alternator**

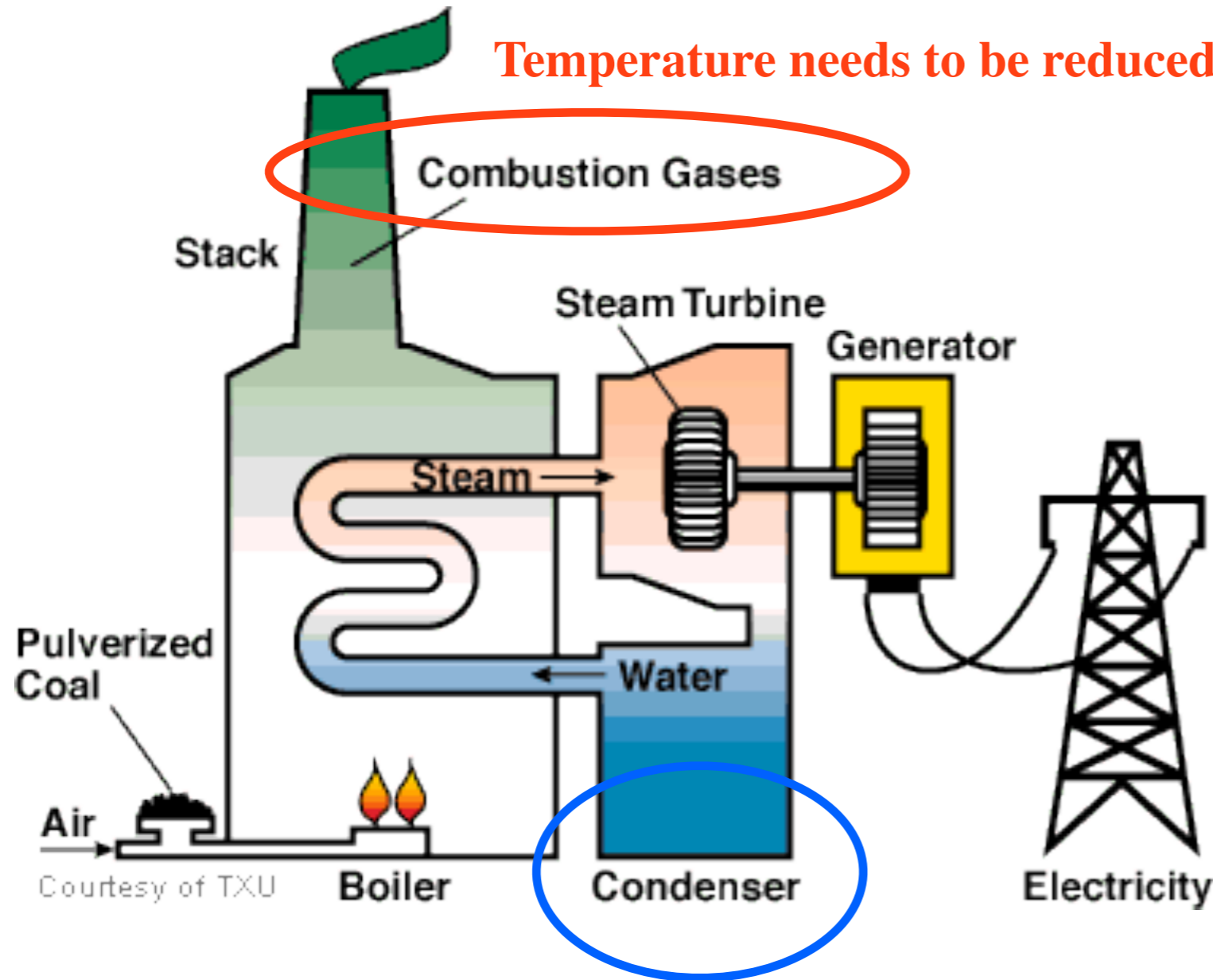
**microfluidic  
sensor**



- **Spin out from Glasgow: Mode Diagnostic**
- **Microfluidic lab-on-a-chip for blood analysis in the gut with integrated wireless readout**
- **Battery powered but issue of toxic materials in batteries and limited lifetime**
- **Can thermoelectrics be used in the future?**

# Energy Conversion: Electricity: The Rankine Cycle

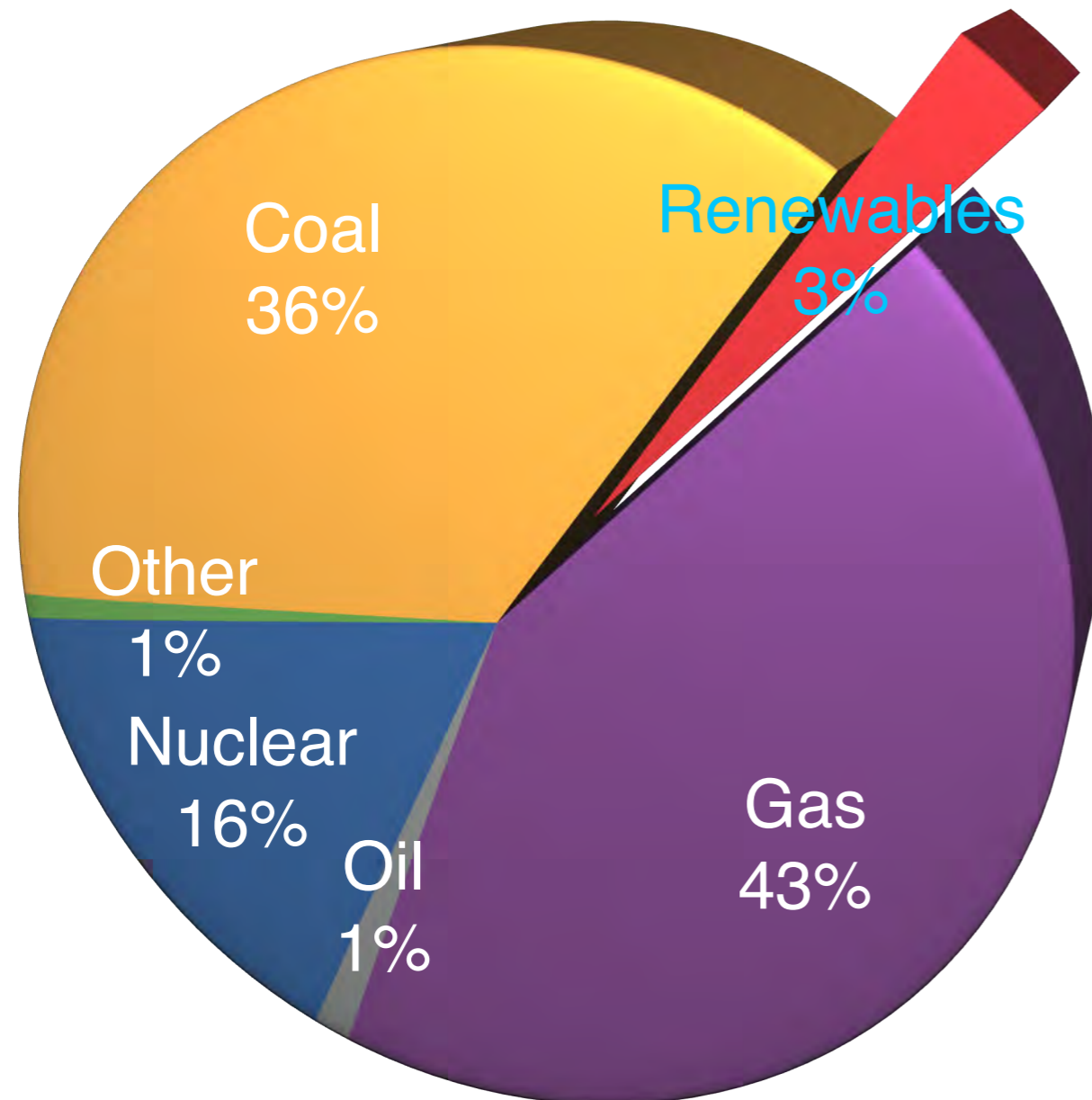
Temperature needs to be reduced by 80 °C for carbon capture



Cooling towers → throw heat away → added losses

Energy stored in fuel → heat → kinetic energy → electric energy

# U.K. Electricity Generation 2007



- Nuclear
- Other
- Coal
- Renewables
- Gas
- Oil

**80% generate CO<sub>2</sub>**

**97% use the Rankine Cycle**

<http://www.berr.gov.uk/energy/statistics/>

# Energy Density for Materials

Substance	Energy Density (MJ/kg)
$E = \Delta m c^2$	89,876,000,000
H <sub>2</sub> fusion	645,000,000
<sup>235</sup> U fission	88,250,000
Hydrogen	143
Petrol	50
Beech tree	5
TNT	4.61
Lithium ion battery	0.72
Ultra capacitor	0.02
Water in 100 m height dam	0.001
1.75 m wind turbine @ 5 ms <sup>-1</sup>	0.00006



# Main Strategies for Optimising ZT

Reducing thermal conductivity faster than electrical conductivity:

- e.g. skutterudite structure: filling voids with heavy atoms

Low-dimensional structures:

- Increase  $\alpha$  through enhanced DOS  $(\alpha = -\frac{\pi^2}{3q} k_B^2 T \left[ \frac{d \ln(\mu(E)g(E))}{dE} \right]_{E=E_F})$
- Make  $\kappa$  and  $\sigma$  almost independent
- Reduce  $\kappa$  through numerous interfaces to increase phonon scattering

Energy filtering:

- $$\alpha = -\frac{k_B}{q} \left[ \frac{E_c - E_F}{k_B T} + \frac{\int_0^\infty \frac{(E - E_c)}{k_B T} \sigma(E) dE}{\int_0^\infty \sigma(E) dE} \right]$$
 enhance  
*Y.I. Ravich et al., Phys. Stat. Sol. (b) 43, 453 (1971)*



# Length Scales: Mean Free Paths

3D electron mean free path  $\ell = v_F \tau_m = \frac{\hbar}{m^*} (3\pi^2 n)^{\frac{1}{3}} \frac{\mu m^*}{q}$

$$\ell = \frac{\hbar \mu}{q} (3\pi^2 n)^{\frac{1}{3}}$$

3D phonon mean free path

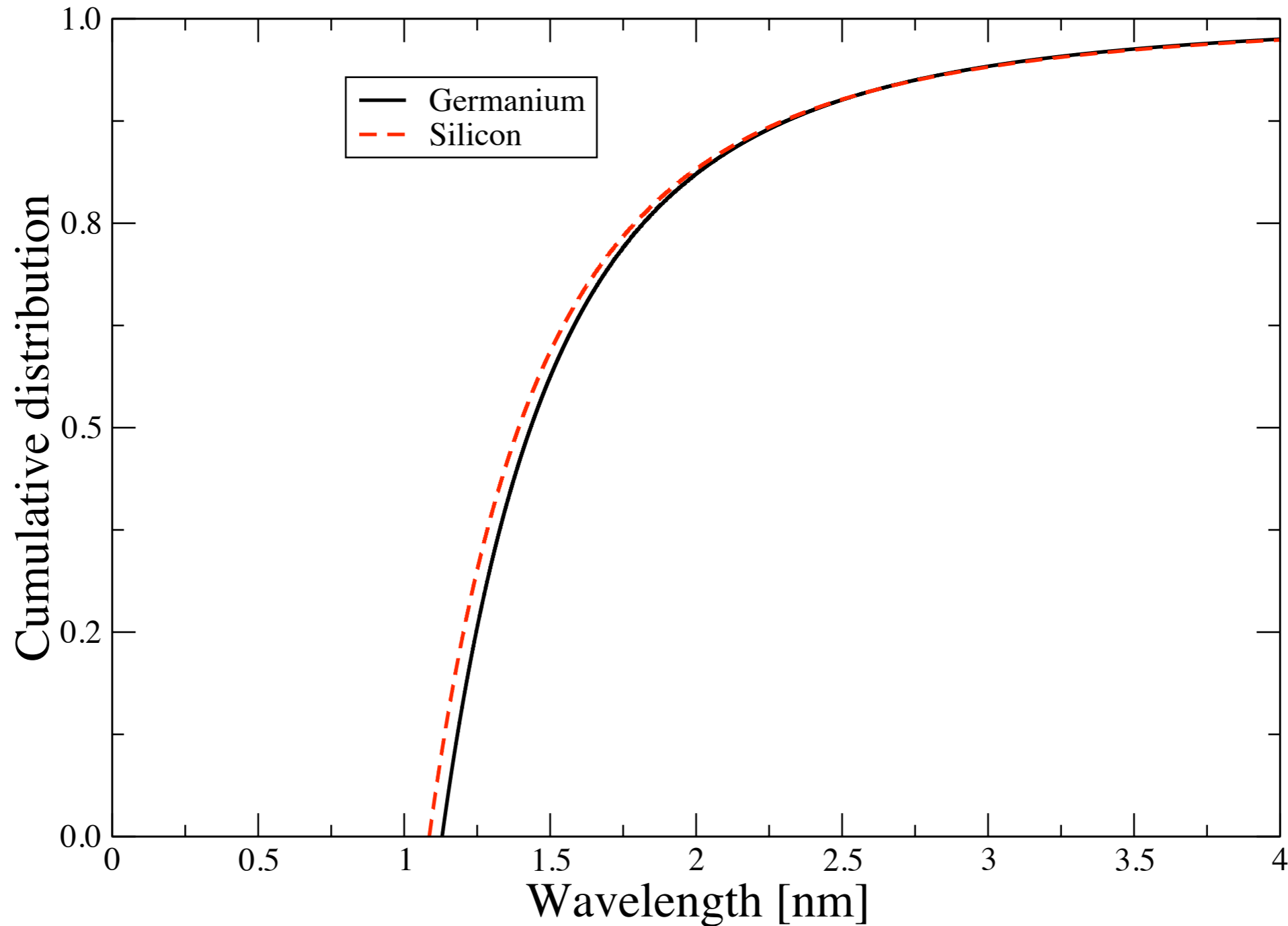
$$\Lambda_{\text{ph}} = \frac{3\kappa_{\text{ph}}}{C_v \langle v_t \rangle \rho}$$

- $C_v$  = specific heat capacity
  - $\langle v_t \rangle$  = average phonon velocity
  - $\rho$  = density of phonons
- A structure may be 2D or 3D for electrons but 1 D for phonons (or vice versa!)

# Phonon Mean Free Paths

Material	Model	Specific Heat ( $\times 10^6 \text{ Jm}^{-3}\text{K}^{-1}$ )	Group velocity ( $\text{ms}^{-1}$ )	Phonon mean free path, $\Lambda_{\text{ph}}$ (nm)
Si	Debye	1.66	6400	40.9
Si	Dispersion	0.93	1804	260.4
Ge	Debye	1.67	3900	27.5
Ge	Dispersion	0.87	1042	198.6

*G. Chen, Phys. Rev. B 57, 14958 (1998)*



**Greater than 95% of heat conduction in Si / Ge from phonons with wavelengths between 1.2 and 3.5 nm**

# Phonon Enhancements

## Phonon scattering:

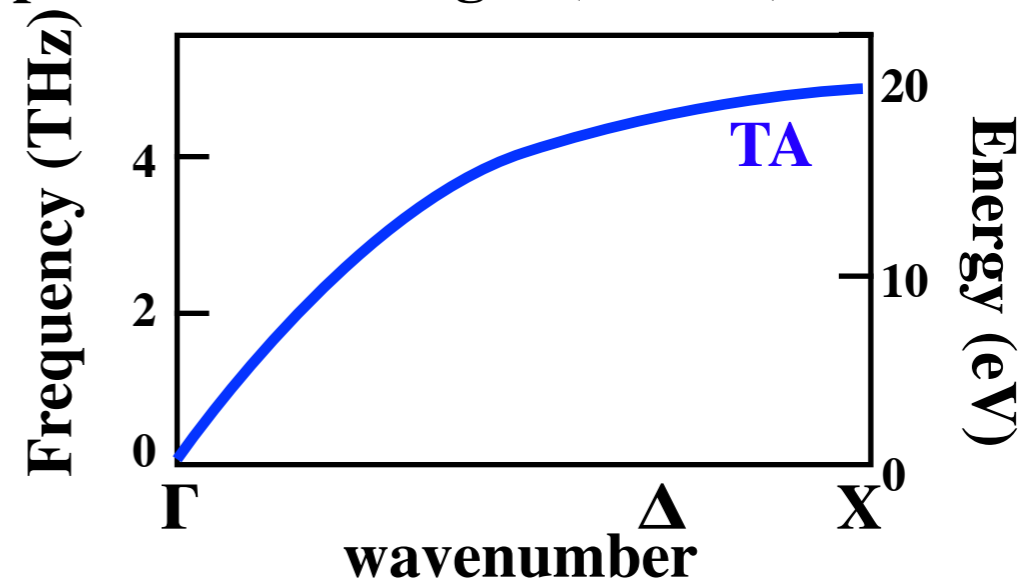
- Require structures below the phonon mean free path

## Phonon Bandgaps:

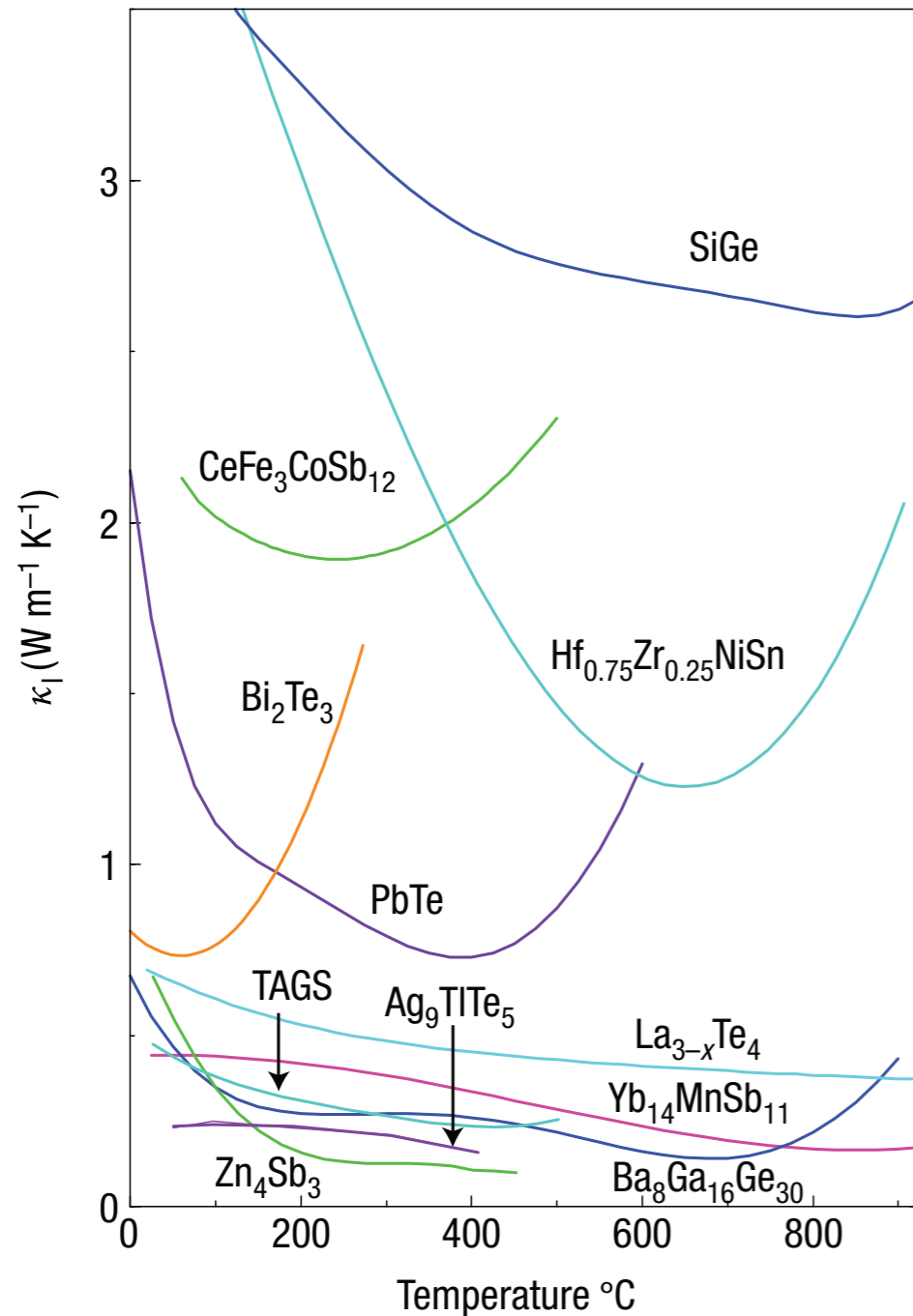
- Change the acoustic phonon dispersion → stationary phonons or bandgaps

- Require structures with features at the phonon wavelength (< 5 nm)

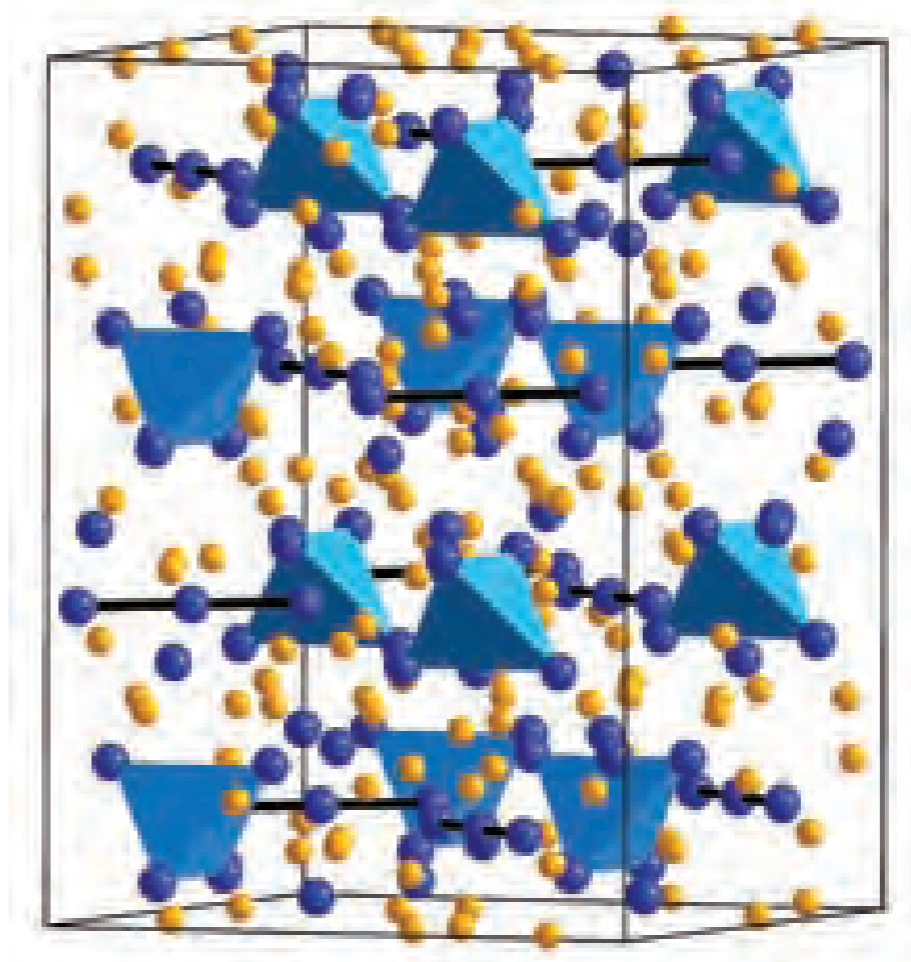
- Phonon group velocity  $\propto \frac{dE}{dk_q}$



# Complex Crystal Structures: Reducing $\kappa_{ph}$



Skutterudite structure: filling voids with heavy atoms

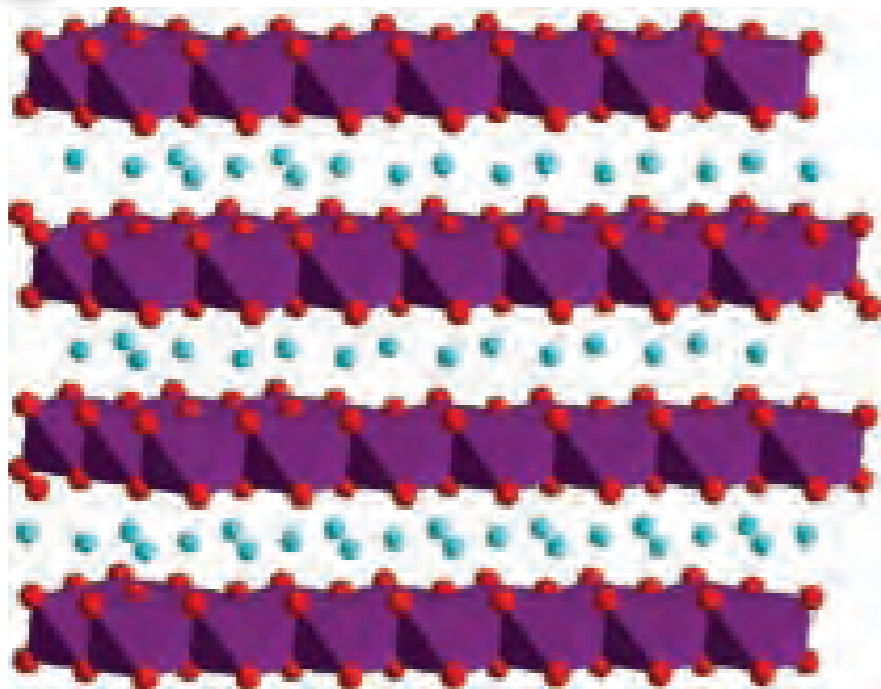


**p-Yb<sub>14</sub>MnSb<sub>11</sub> – ZT ~ 1 @ 900 °C**

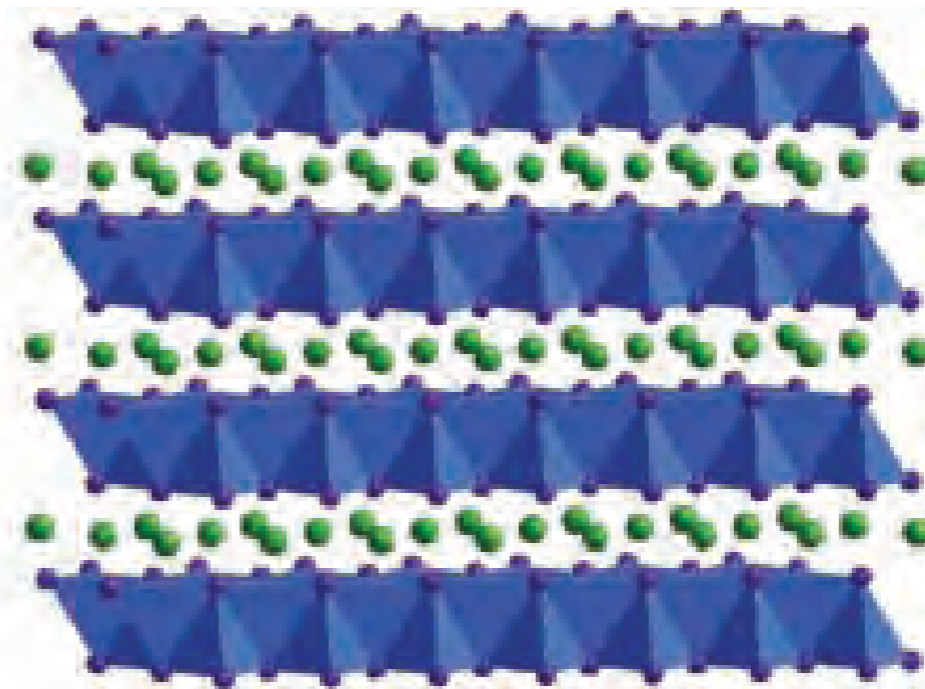
*G.J. Snyder et al., Nat. Mat. 7, 105 (2008)*

# Electron Crystal – Phonon Glass Materials

- Principle: trying to copy “High  $T_c$ ” superconductor structures
- Heavy ion / atom layers for phonon scattering
- High mobility electron layers for high electrical conductivity



$\text{Na}_x\text{CoO}_2$

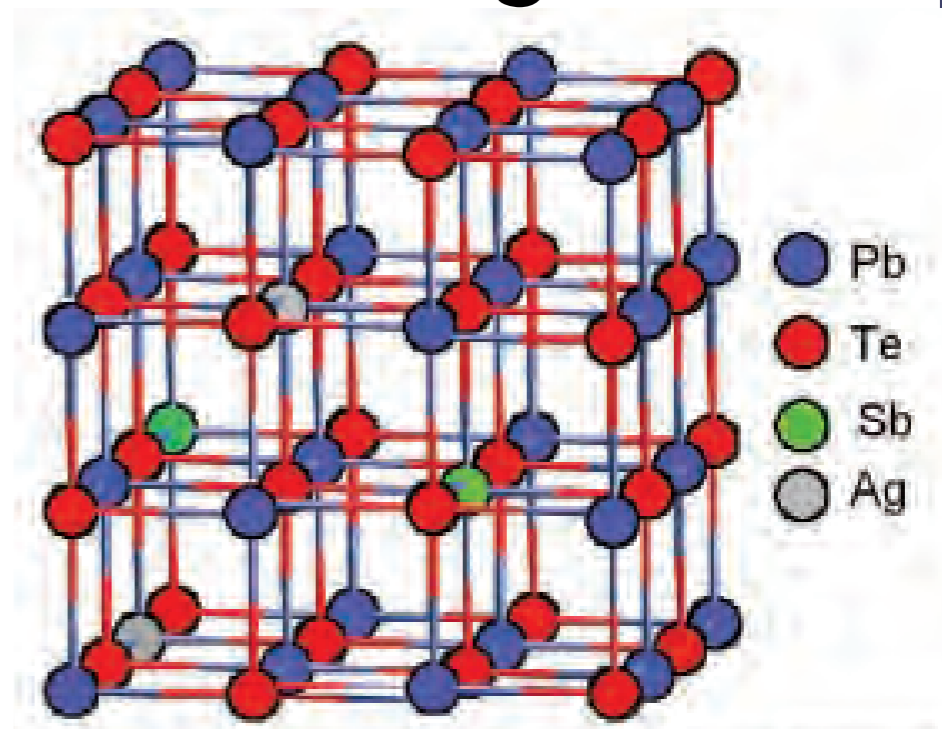
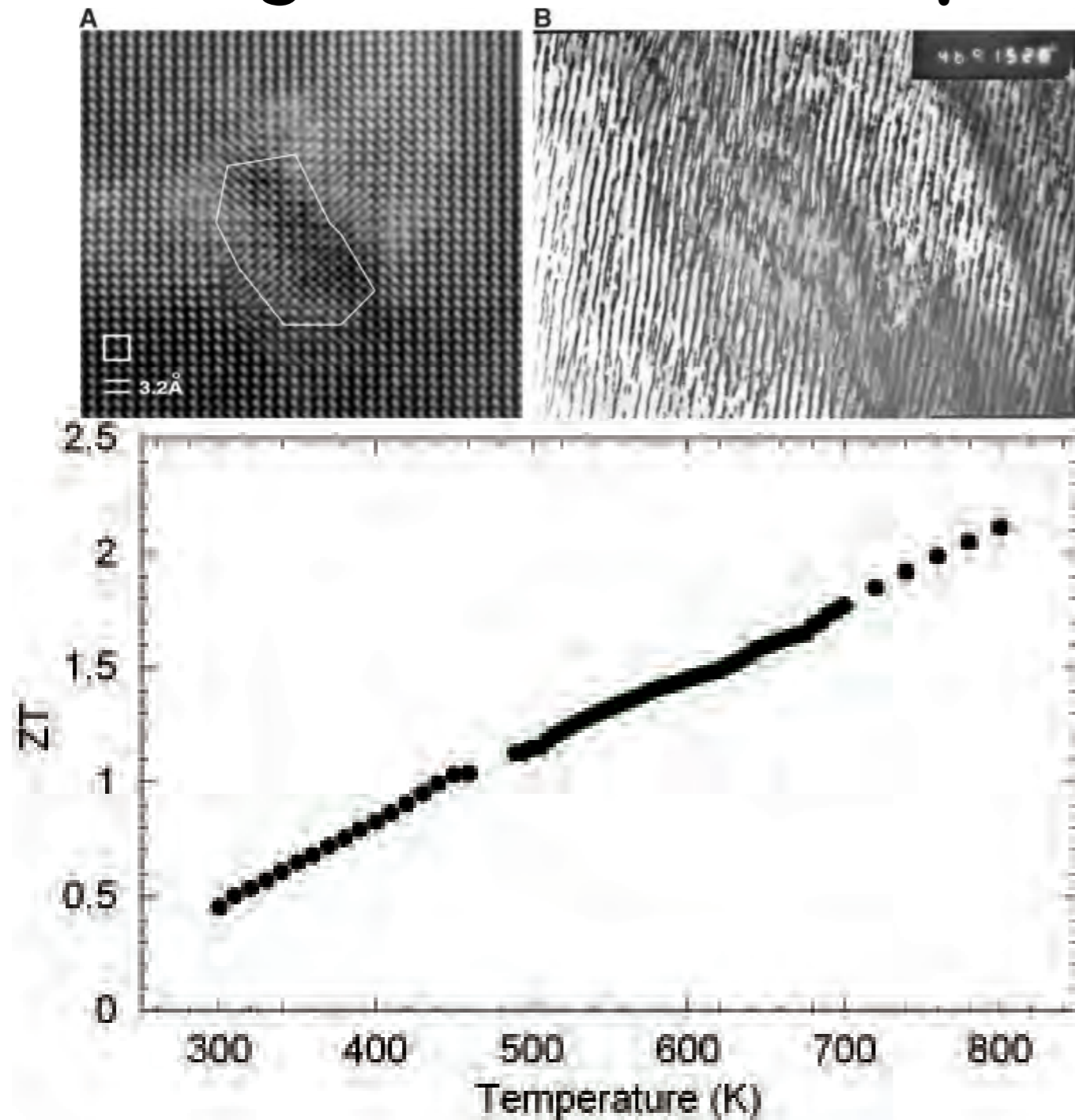


$\text{Ca}_x\text{Yb}_{1-x}\text{Zn}_2\text{Sb}_2$

- Only small improvements to ZT observed

*G.J. Snyder et al., Nat. Mat. 7, 105 (2008)*

# AgPb<sub>18</sub>SbTe<sub>20</sub> – Nanoparticle Scattering?



$$\alpha = -335 \mu\text{VK}^{-1}$$
$$\sigma = 30,000 \text{ S/m}$$
$$\kappa = 1.1 \text{ Wm}^{-1}\text{K}^{-1}$$

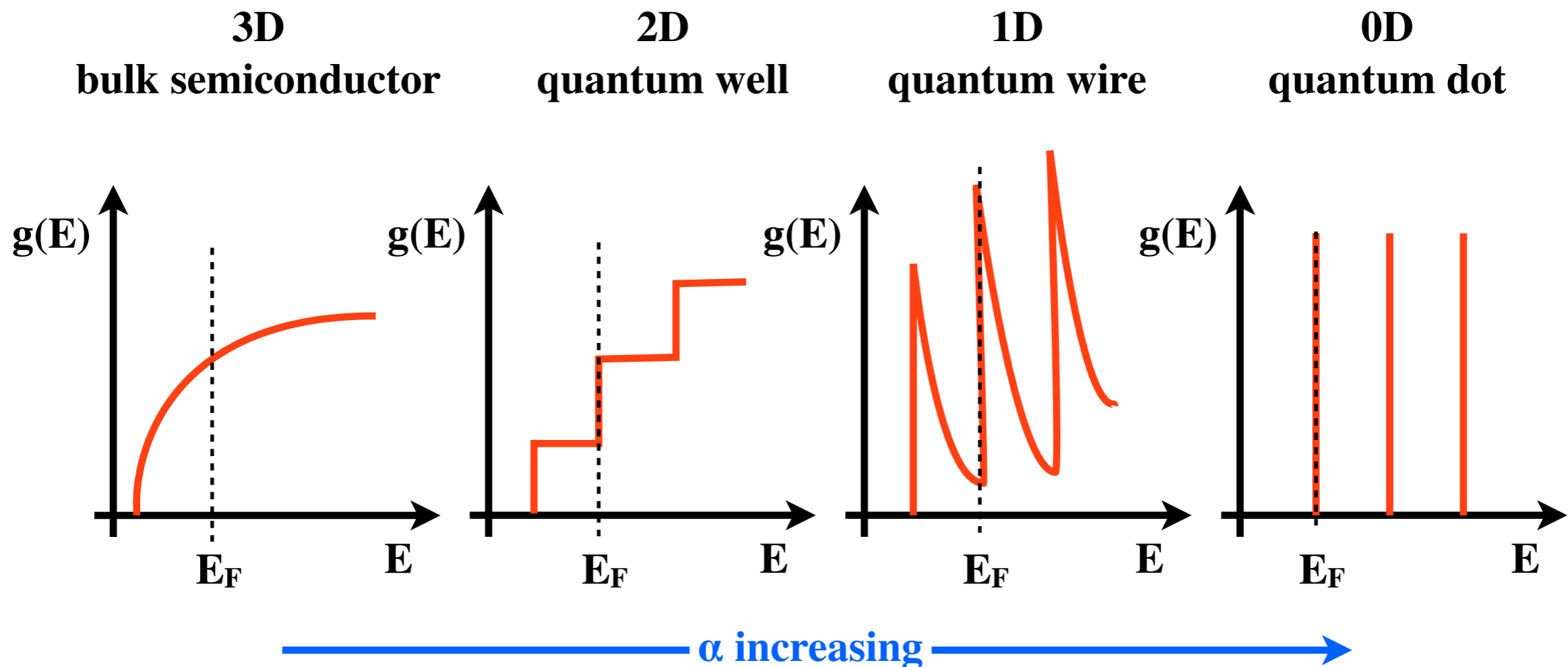
at 700 K

*K.F. Hsu et al., Science 303, 818 (2004)*

# Seebeck Enhancement at Low Dimensions

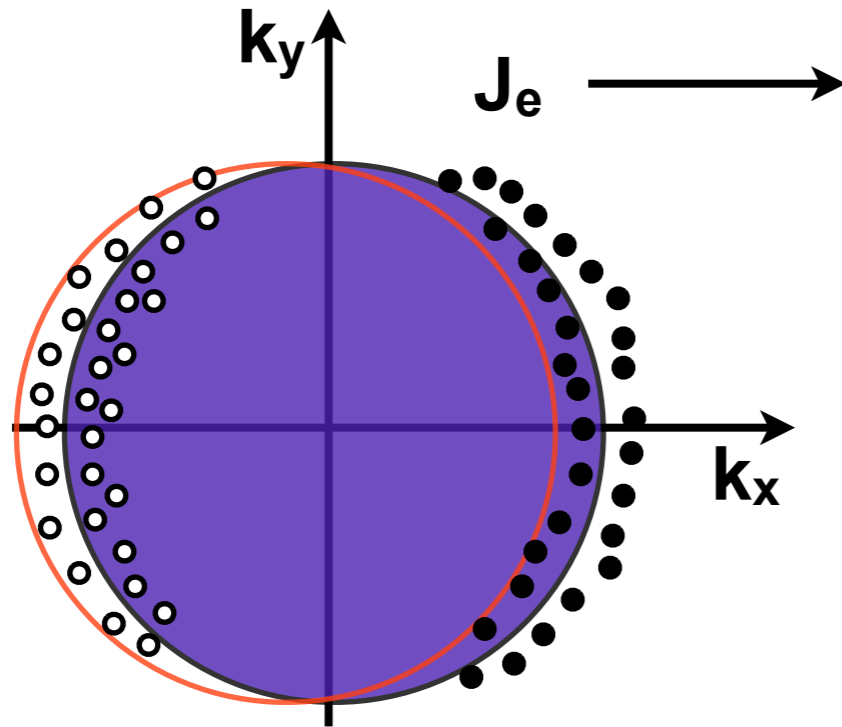
- Increase  $\alpha$  through enhanced DOS:

$$\alpha = -\frac{\pi^2}{3q} k_B^2 T \left[ \frac{d \ln(\mu(E)g(E))}{dE} \right]_{E=E_F}$$

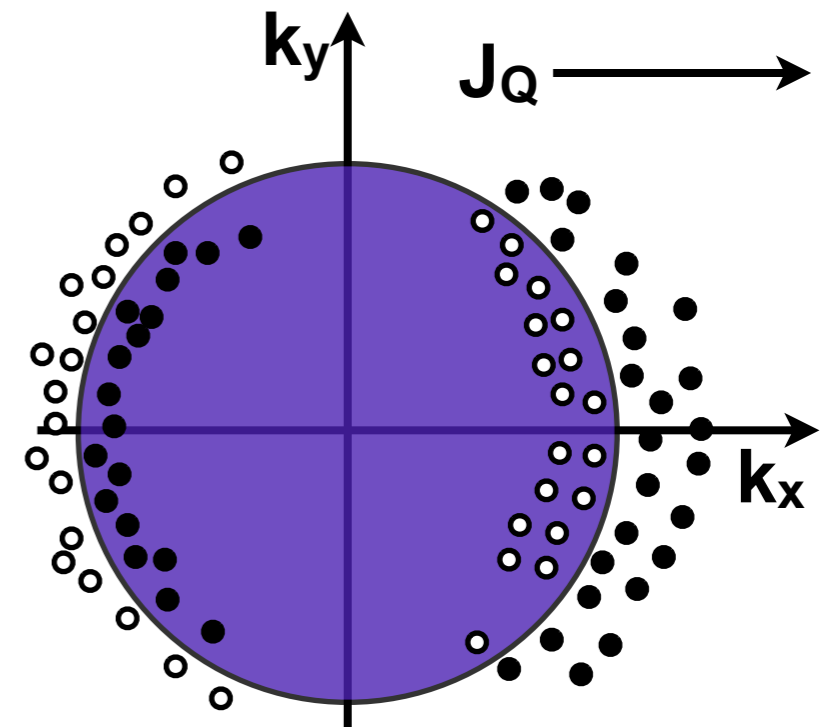




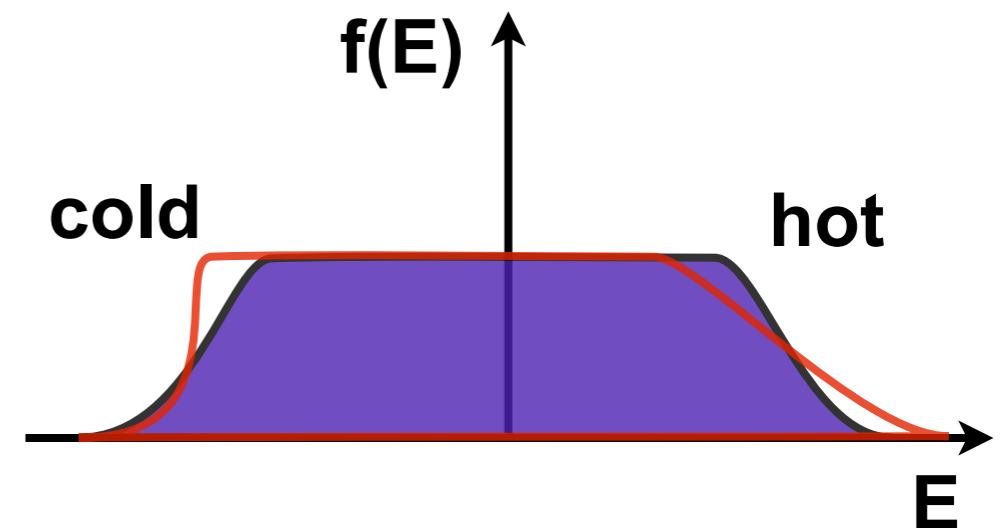
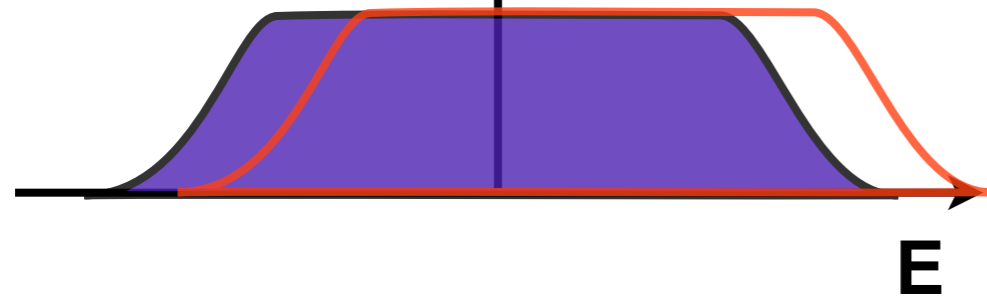
## 2D electronic transport



## 2D thermal transport

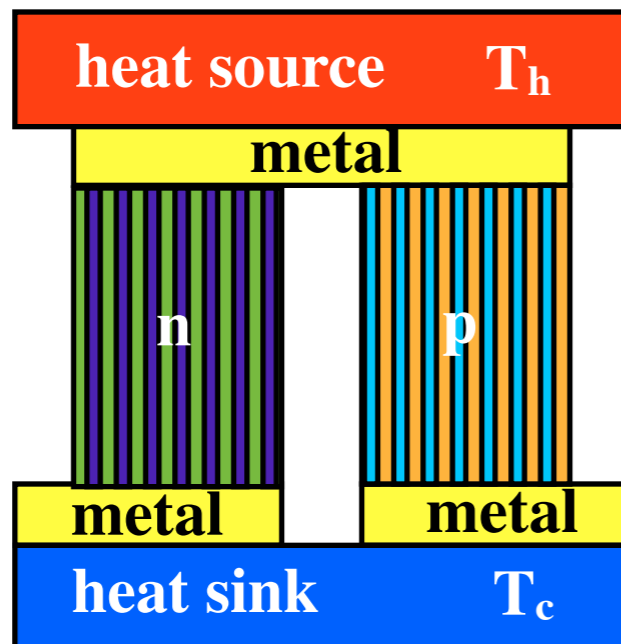


$$f(E) = \frac{1}{\left[1 + \exp\left(\frac{E - E_F}{k_B T}\right)\right]}$$

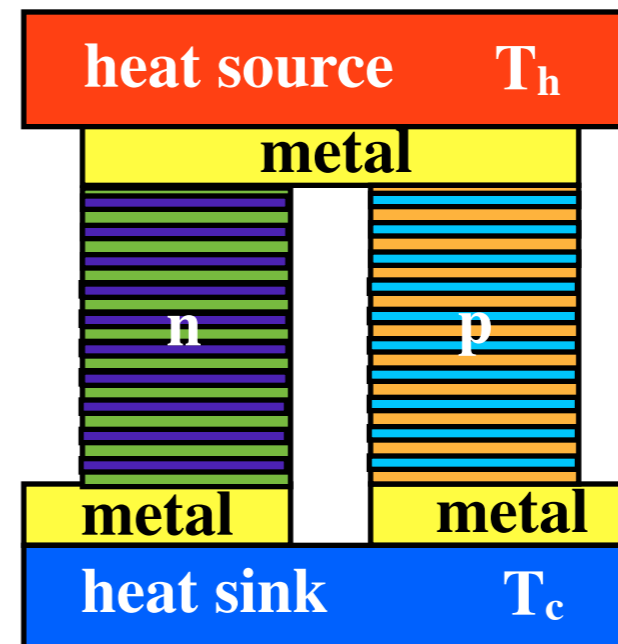


# Thermoelectric Low Dimensional Structures

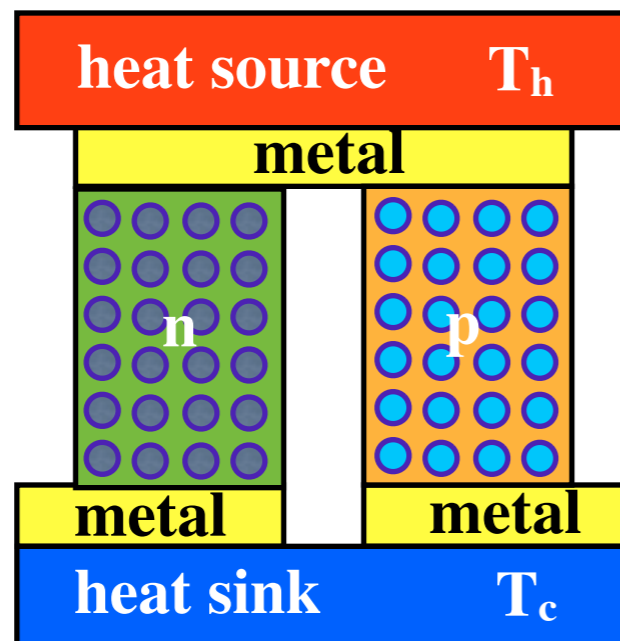
## Lateral superlattice



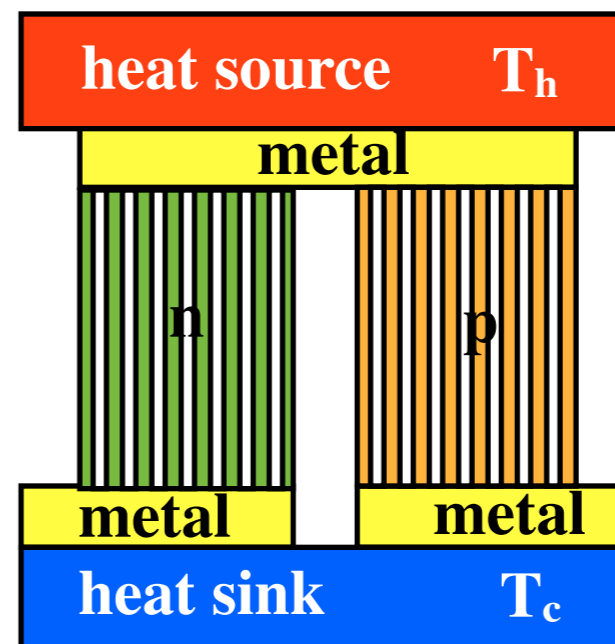
## Vertical superlattice



## Quantum Dots



## Nanowires



# Low Dimensional Structures: 2D Superlattices

- Use of transport along superlattice quantum wells
- Higher  $\alpha$  from the higher density of states
- Higher electron mobility in quantum well  $\rightarrow$  higher  $\sigma$
- Lower  $\kappa_{ph}$  through additional phonon scattering from heterointerfaces
- Disadvantage: higher  $\kappa_{el}$  with higher  $\sigma$  (but layered structure can reduce this effect)
- Overall  $Z$  and  $ZT$  should increase

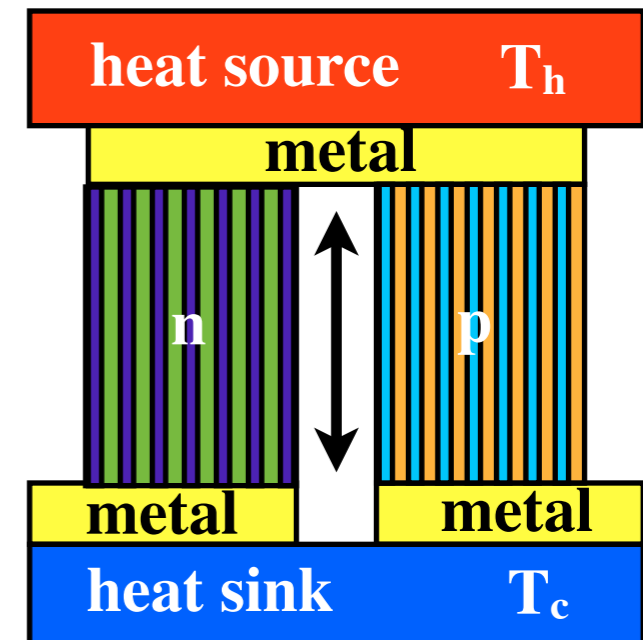


Figure of merit

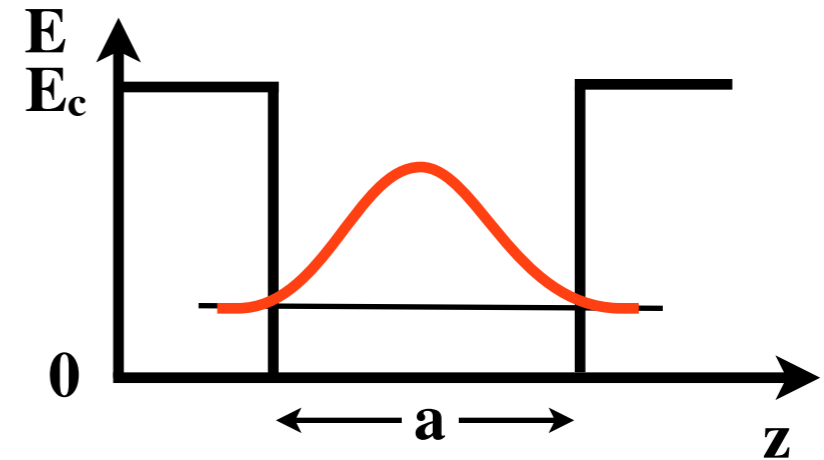
$$ZT = \frac{\alpha^2 \sigma}{\kappa} T$$

*EHC Parker and TE Whall, 1987*

*L.D. Hicks and M.S. Dresselhaus, Phys. Rev. B 47, 12737 (1993)*

# 2D Bi<sub>2</sub>Te<sub>3</sub> Superlattices

- $E_{F2D} = E_{F3D} - \frac{\hbar^2 \pi^2}{2m_z^* a^2}$
- Both doping and quantum well width,  $a$  can now be used to engineer ZT



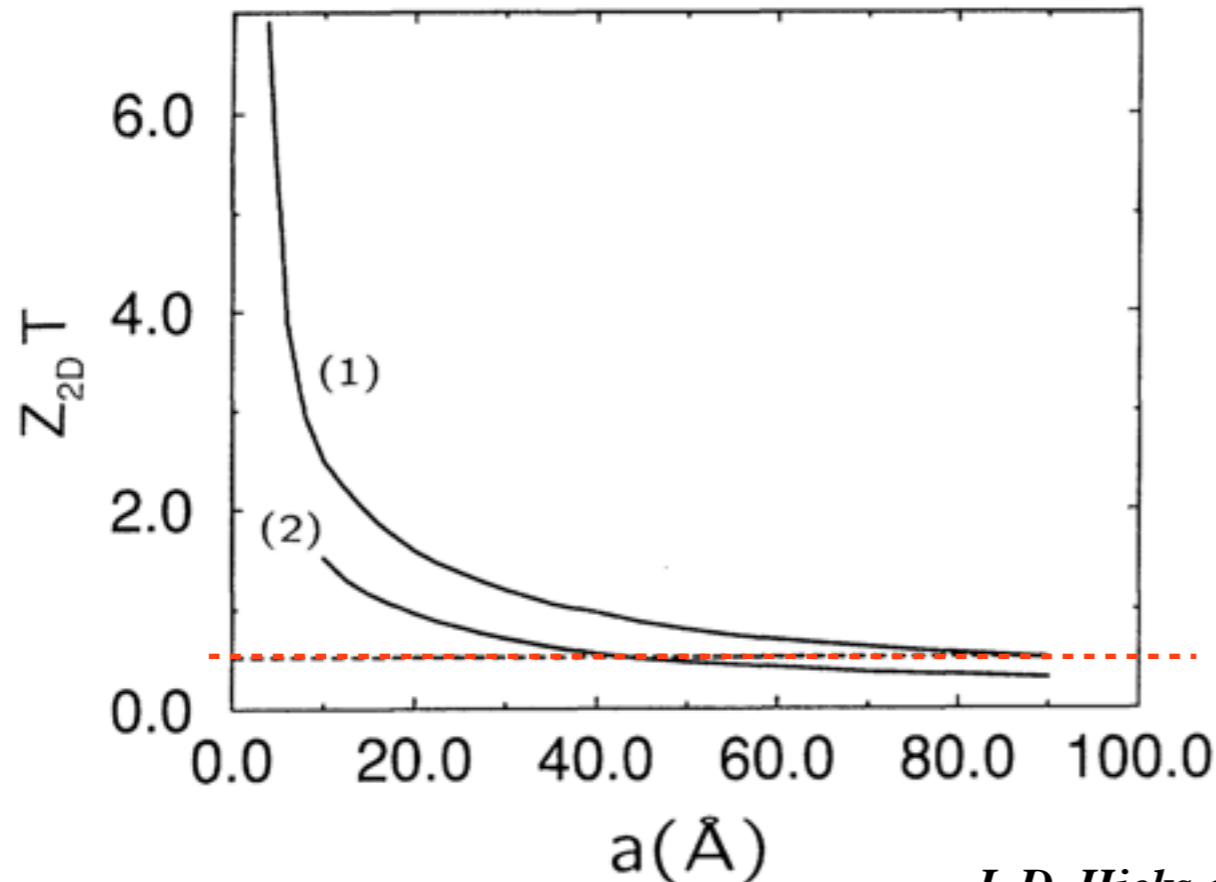
$$m_x = 0.021 m_0$$

$$m_y = 0.081 m_0$$

$$m_z = 0.32 m_0$$

$$\kappa_{ph} = 1.5 \text{ Wm}^{-1}\text{K}^{-1}$$

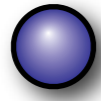
$$\mu_{a0} = 0.12 \text{ m}^2\text{V}^{-1}\text{s}^{-1}$$



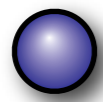
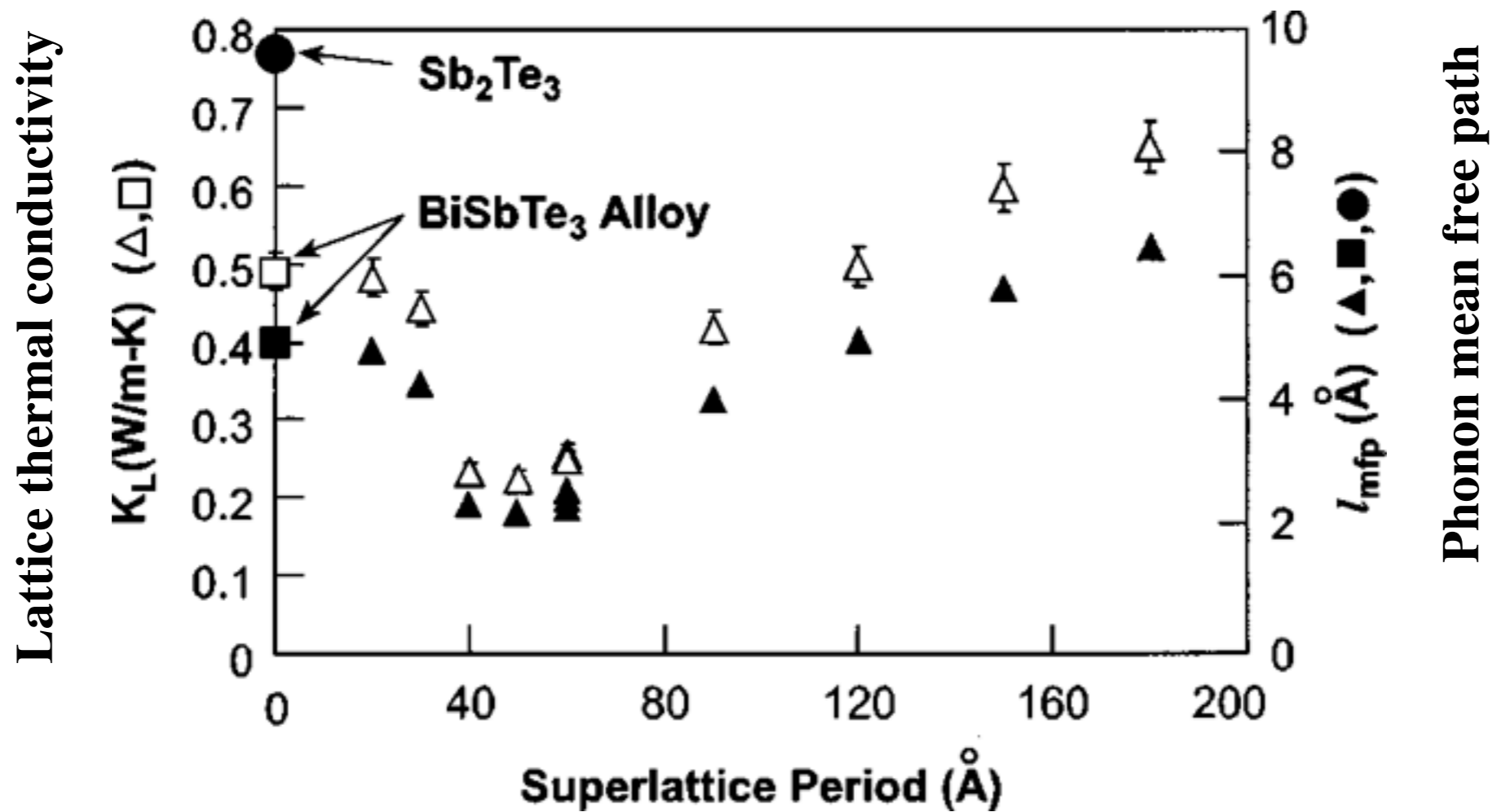
ZT for 3D Bi<sub>2</sub>Te<sub>3</sub>

*L.D. Hicks and M.S. Dresselhaus, Phys. Rev. B 47, 12737 (1993)*

# p-Bi<sub>2</sub>Te<sub>3</sub> / Sb<sub>2</sub>Te<sub>3</sub> Superlattices



Bi<sub>2</sub>Te<sub>3</sub>  $\kappa_{ph} = 1.05 \text{ Wm}^{-1}\text{K}^{-1}$



3/3 nm, 1/5 nm, 2/4 nm Bi<sub>2</sub>Te<sub>3</sub> / Sb<sub>2</sub>Te<sub>3</sub> periods almost identical  $\kappa_{ph}$

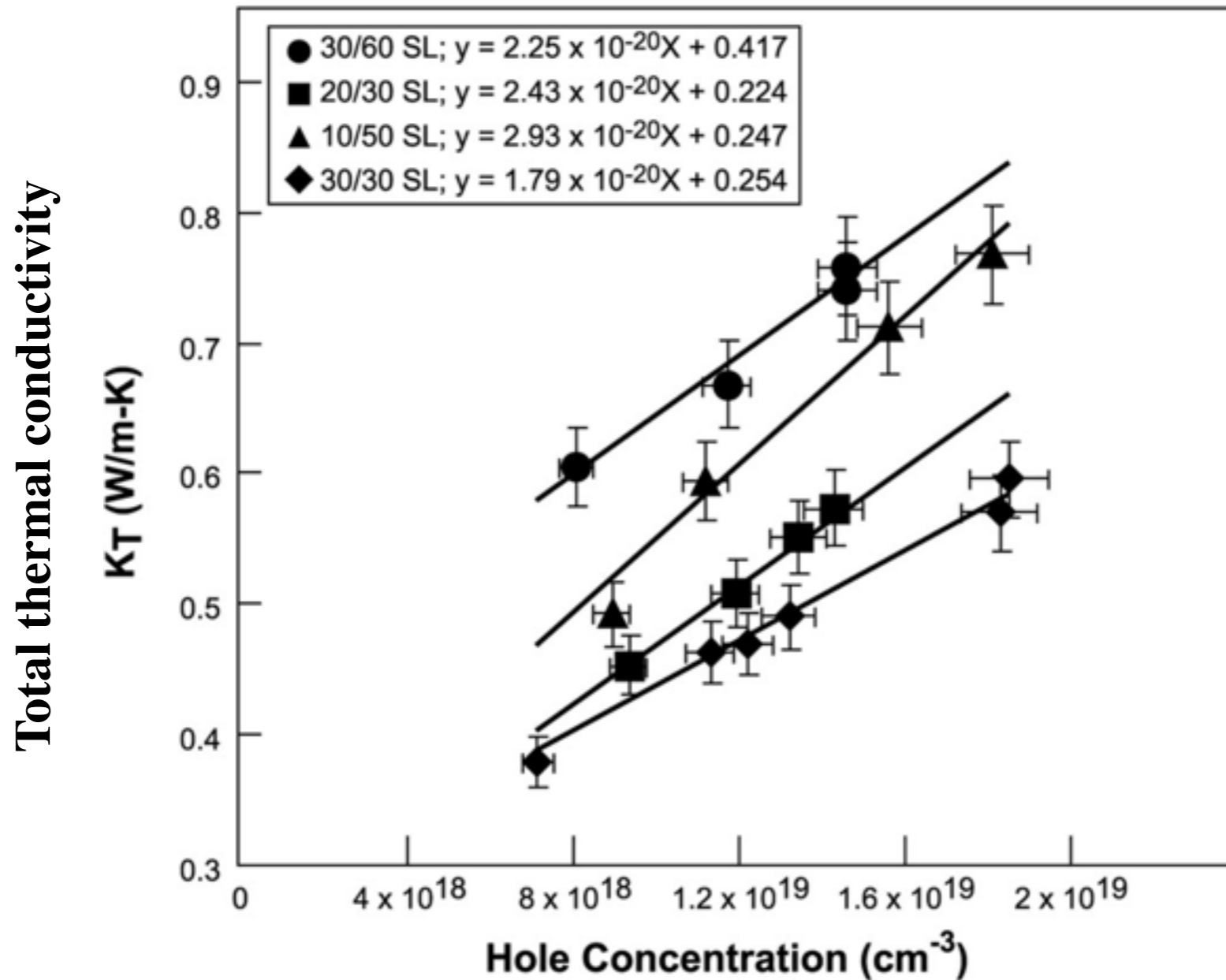
*R. Venkatasubramaniam Phys. Rev. B 61, 3091 (2000)*

# p-Bi<sub>2</sub>Te<sub>3</sub> / Sb<sub>2</sub>Te<sub>3</sub> Superlattices



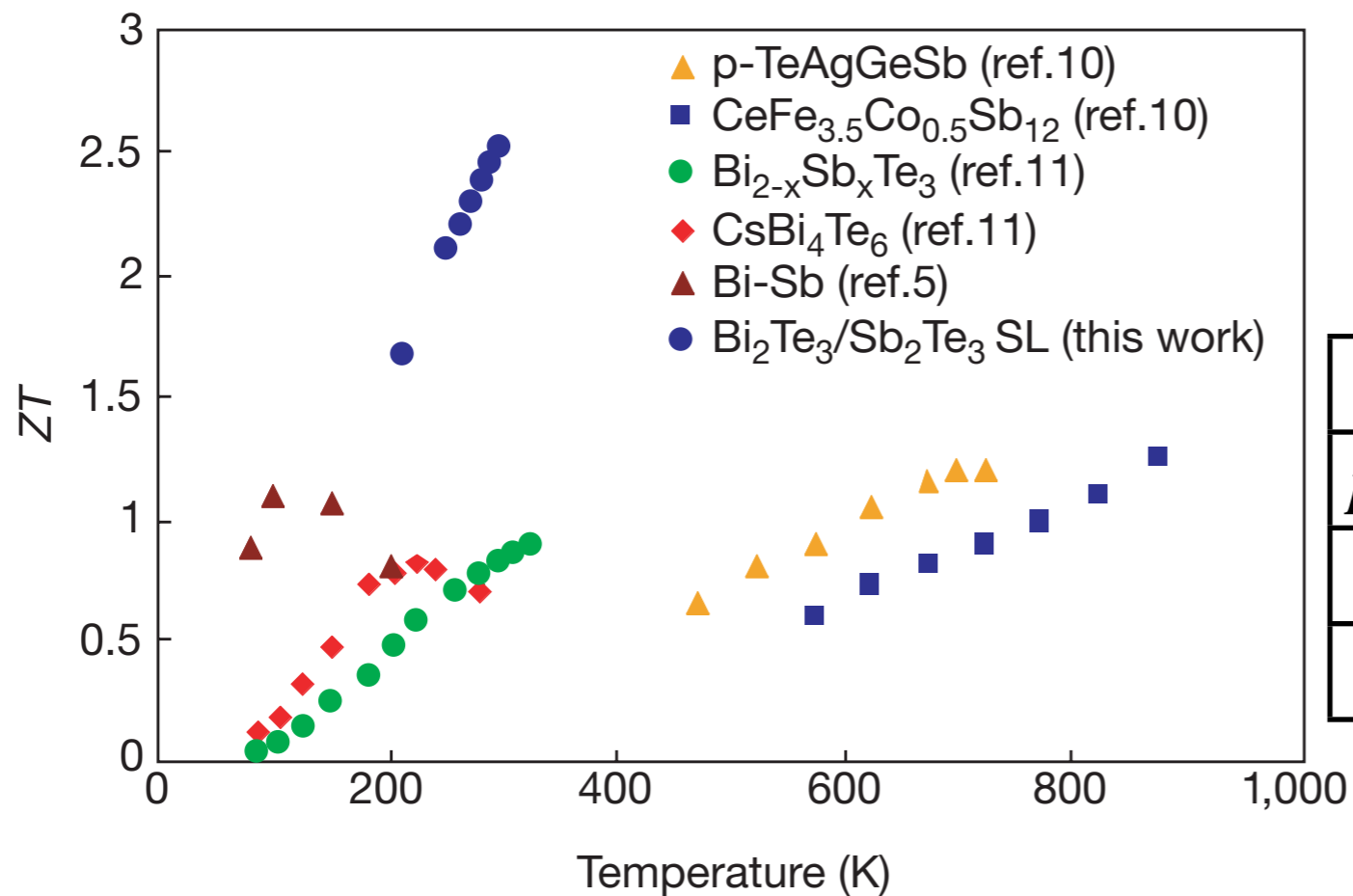
Bi<sub>2</sub>Te<sub>3</sub>  $\kappa_{ph} = 1.2 \text{ Wm}^{-1}\text{K}^{-1}$

*C.B. Satterthwaite, et al. Phys. Rev. 108: 1164 (1957)*



*R. Venkatasubramaniam Phys. Rev. B 61, 3091 (2000)*

# p-Bi<sub>2</sub>Te<sub>3</sub> / Sb<sub>2</sub>Te<sub>3</sub> Superlattices



**Bulk Bi<sub>2</sub>Te<sub>3</sub> ZT ~ 1.0**

**Superlattice ZT = 2.6**

Electrons	Phonons
$\mu = 383 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$	
$l = 11.4 \text{ nm}$	$\Lambda_{\text{ph}} = 3 \text{ nm}$
$k_{\text{el}} l \sim 7.6$	$k_{\text{ph}} \Lambda \sim 0.5$

**=> Phonon blocking**



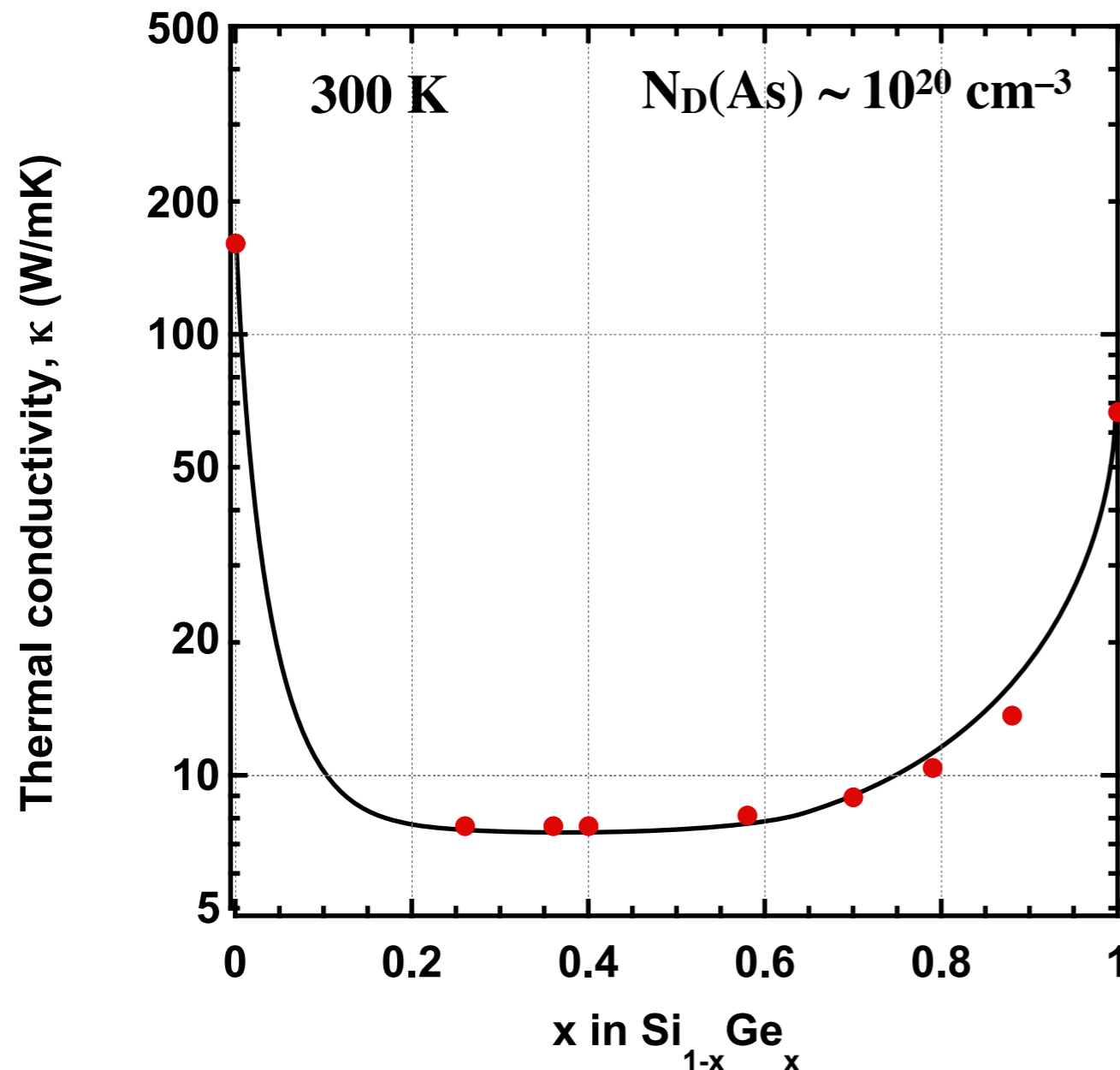
**1 nm: 5 nm p-Bi<sub>2</sub>Te<sub>3</sub> QW / Sb<sub>2</sub>Te<sub>3</sub> barrier superlattices**



**Thermal conductivity reduced more than electrical conductivity**

*R. Venkatasubramanian et al., Nature 413, 597 (2001)*

# SiGe Thermal Conductivity

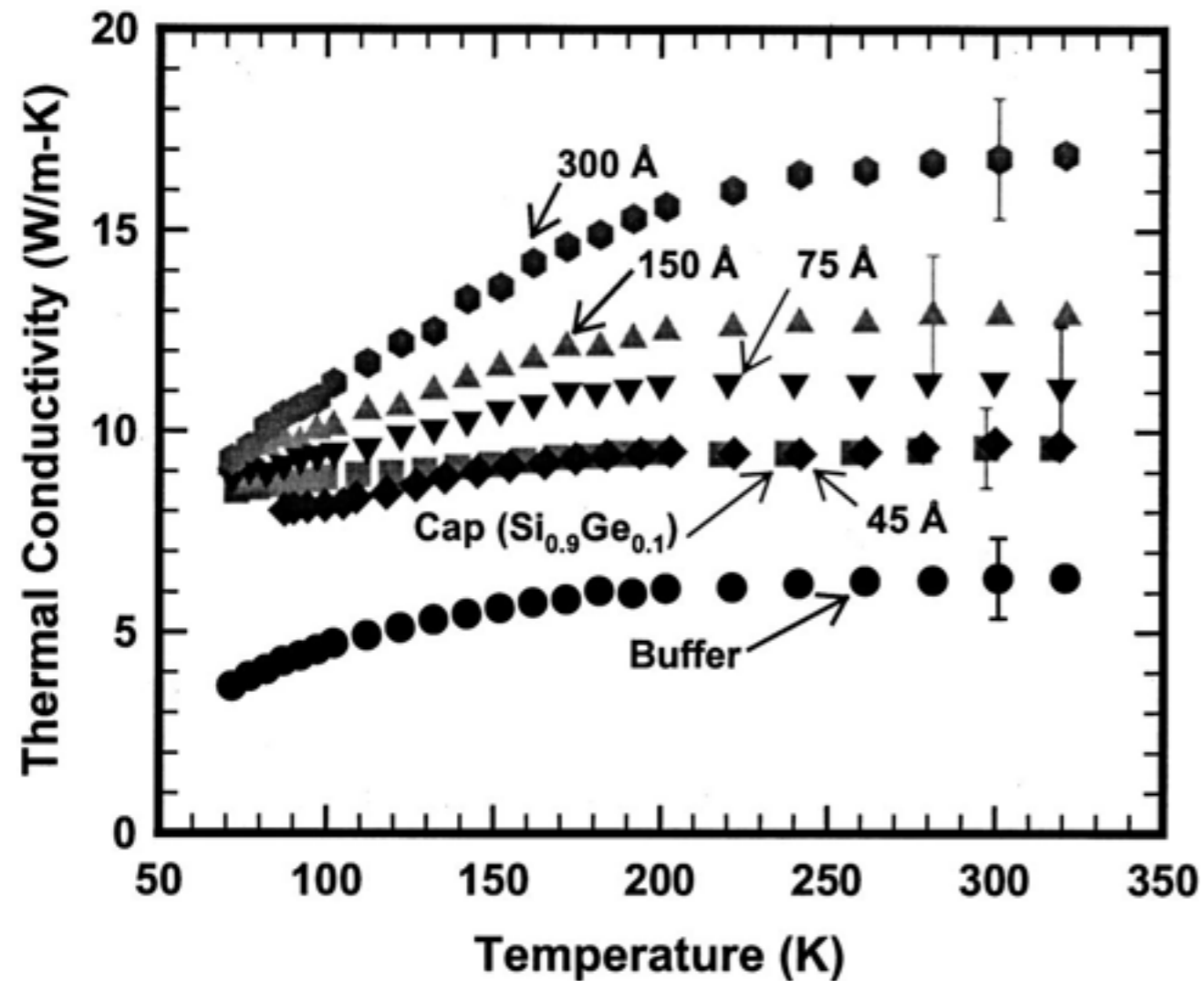


- Lower  $\kappa$  in alloy through additional phonon scattering
- Electron / hole mobility - small reduction by alloy scattering
- Effect ideal for engineering thermoelectric materials

*J.P. Dismukes et al., J. Appl. Phys. 35, 2899 (1964)*



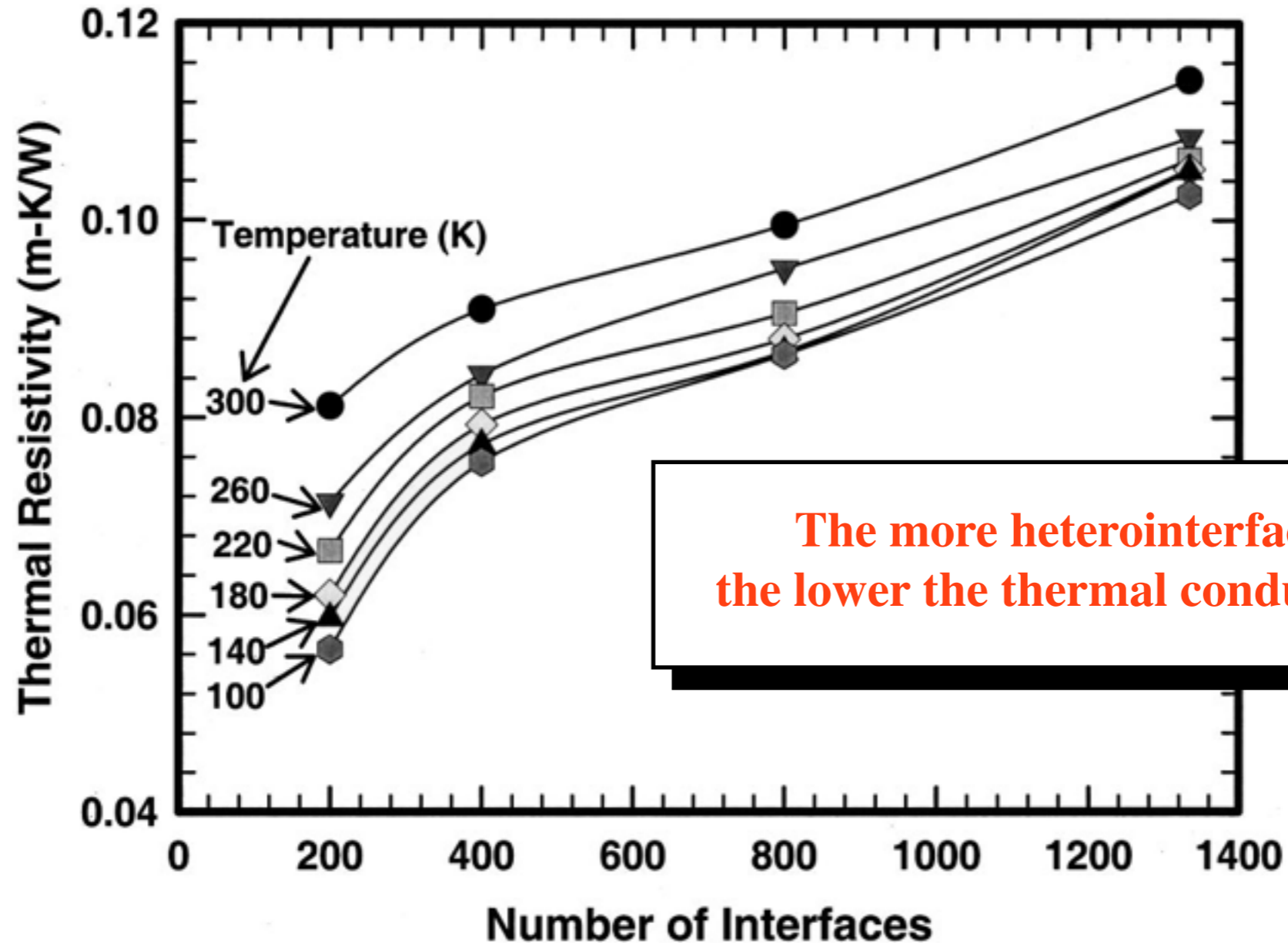
# Thermal Conductivity Si/Si<sub>0.7</sub>Ge<sub>0.3</sub> Superlattices



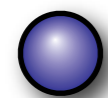
- 2:1 Si to Si<sub>0.7</sub>Ge<sub>0.3</sub>
- Buffer is 1  $\mu\text{m}$  Si<sub>0.9</sub>Ge<sub>0.1</sub>
- $\kappa$  reduces as heterolayer thickness reduces

*S. Huxtable et al., Appl. Phys. Lett. 80, 1737 (2002)*

# Thermal Conductivity Si/Si<sub>0.7</sub>Ge<sub>0.3</sub> Superlattices



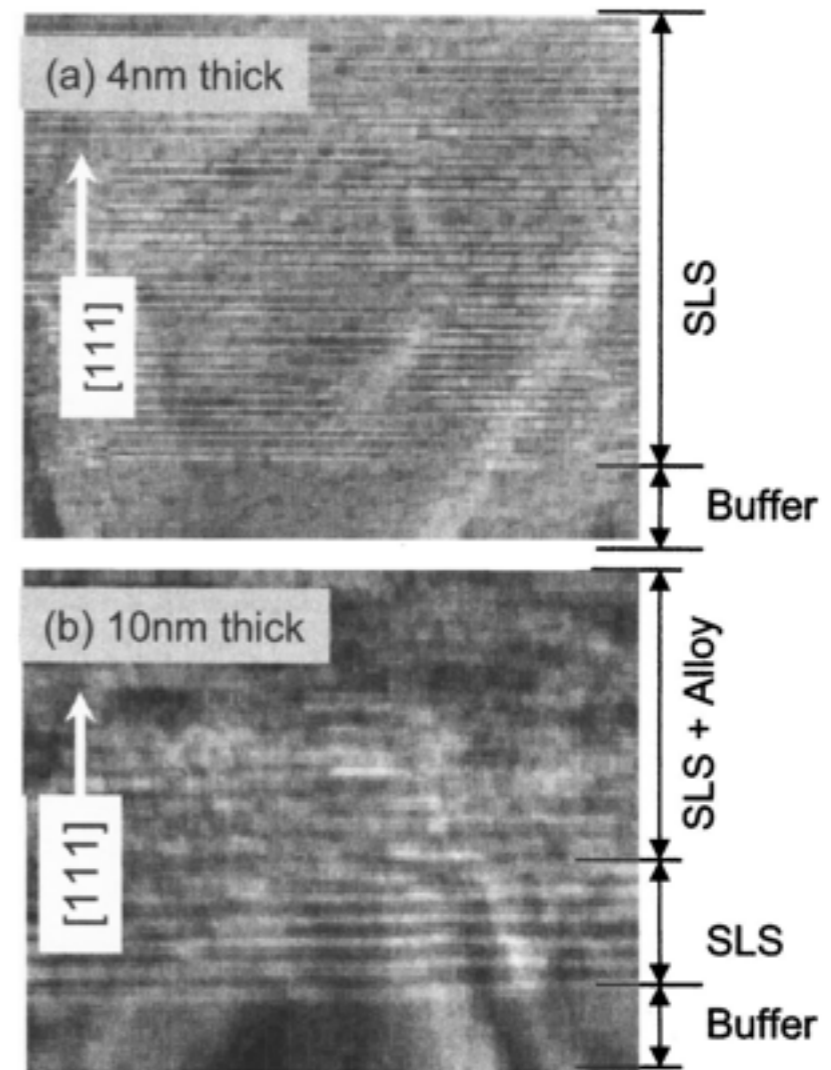
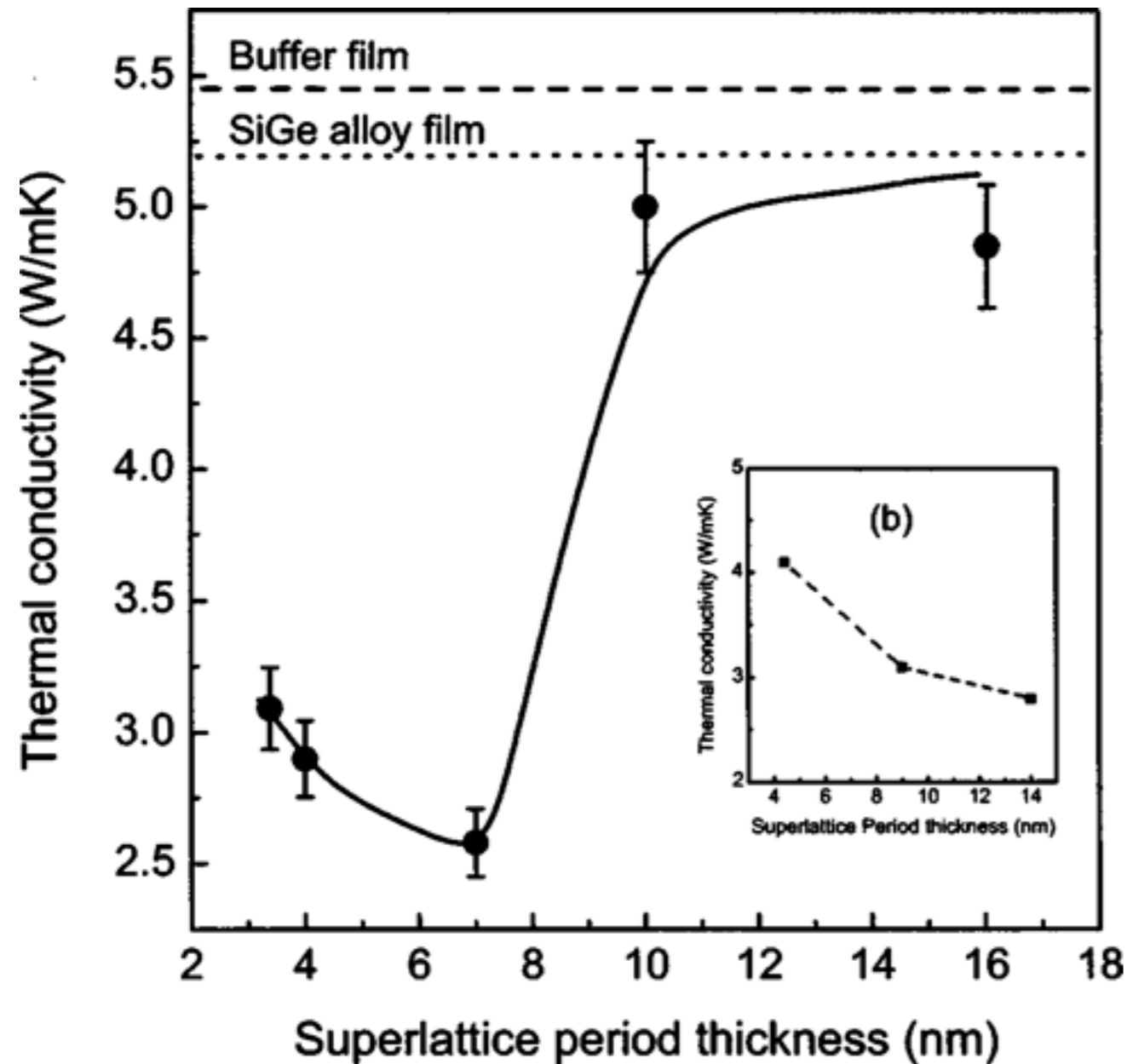
**The more heterointerfaces,  
the lower the thermal conductivity**



Physically: more heterointerfaces → more phonon scattering

*S. Huxtable et al., Appl. Phys. Lett. 80, 1737 (2002)*

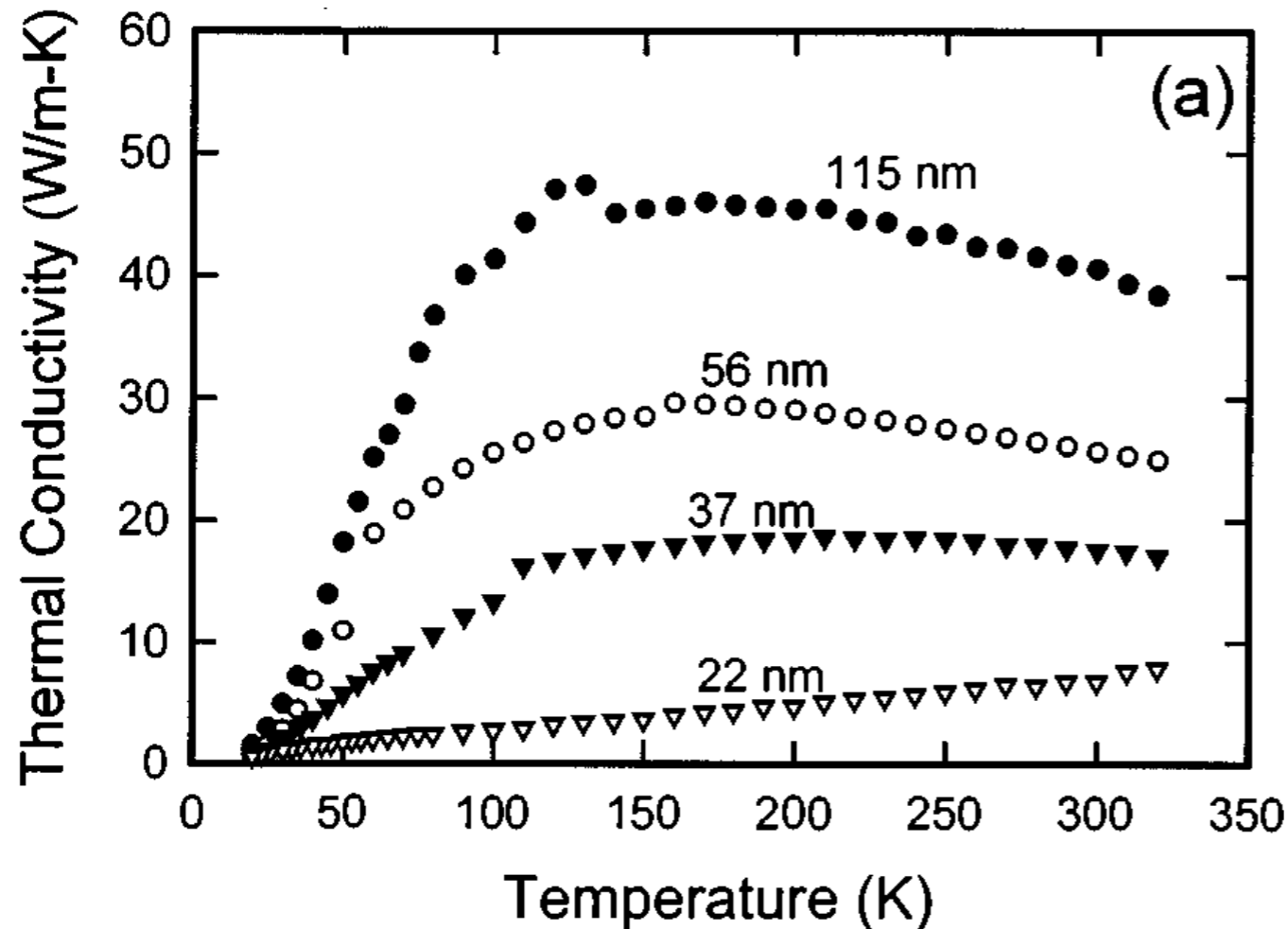
# Si/Ge Superlattice Reduced Thermal Conductivity



$\text{Si}_{0.5}\text{Ge}_{0.5}$  buffer

*S. Chakraborty et al., Appl. Phys. Lett. 83, 4184 (2003)*

# Thermal Conductivity of Silicon Nanowires



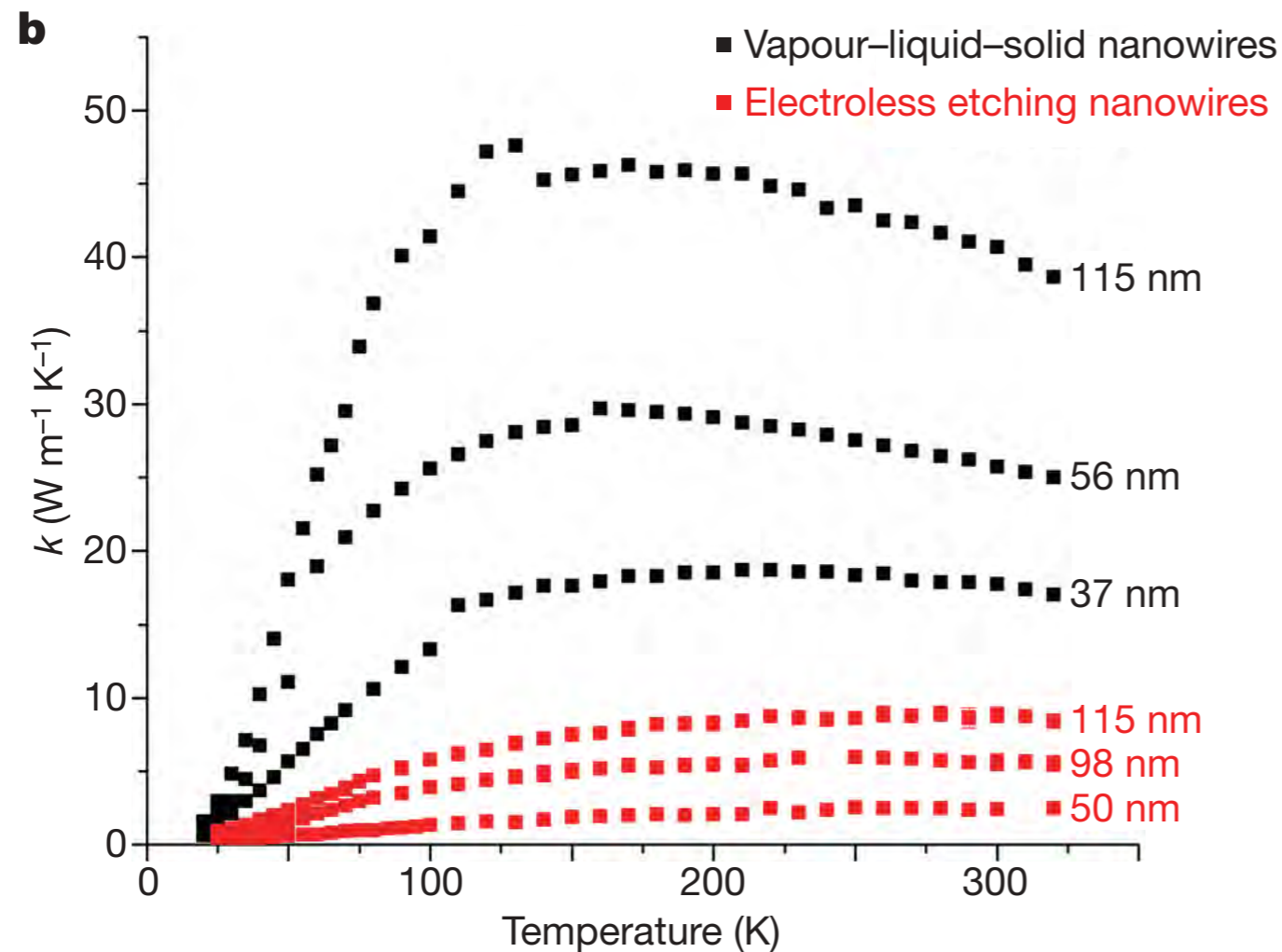
● For bulk Si  
 $\kappa \sim 149 \text{ Wm}^{-1}\text{K}^{-1}$   
 at 300 K

● For bulk Si  
 $\Lambda_{\text{ph}} = \frac{3\kappa_{\text{ph}}}{C_v \langle v_t \rangle \rho}$   
 $\sim 300 \text{ nm}$

● Phonon scattering at boundaries increases for smaller diameter wires

*D.Y. Li et al. Appl. Phys. Lett. 83, 2934 (2003)*

# Thermal Conductivity of 1D Silicon Nanowires



**Red data from nanowires with rough boundaries**

$\Lambda_{\text{ph}} = \frac{3\kappa_{\text{ph}}}{C_v \langle v_t \rangle \rho}$   
 $\sim 300 \text{ nm}$

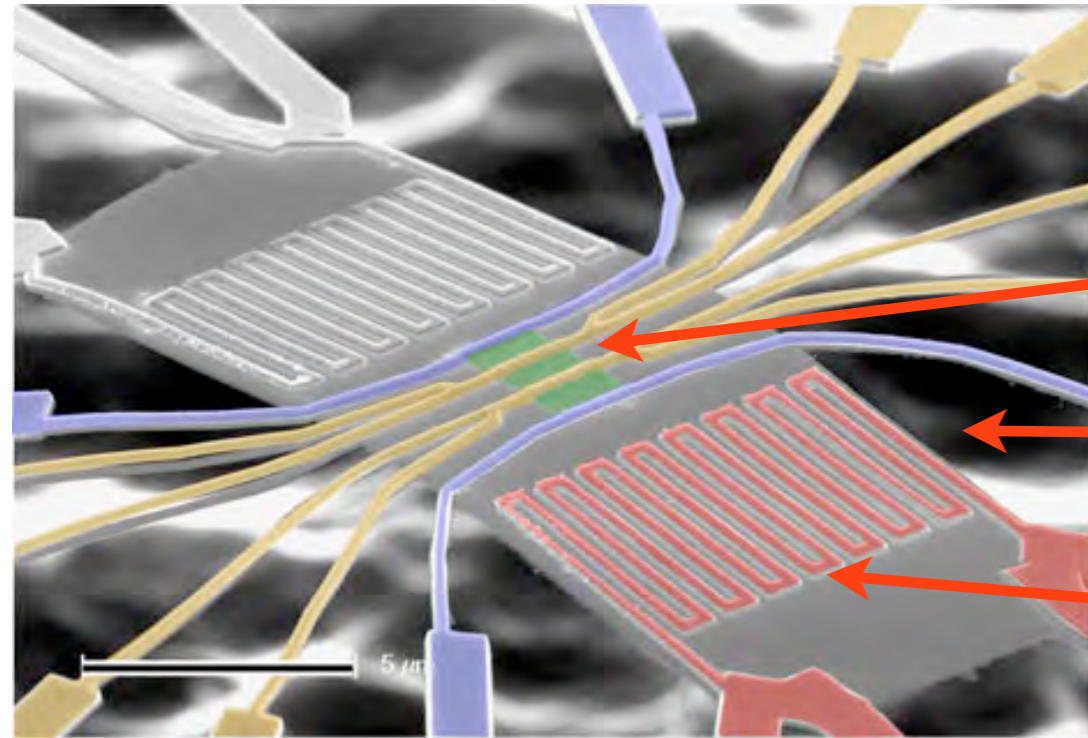
$\ell = 110 \text{ nm}$

Phonon scattering  $\gg$   
 electron scattering

reduces faster than  $\sigma$

*A.I. Hochbaum et al., Nature 451, 163 (2007)*

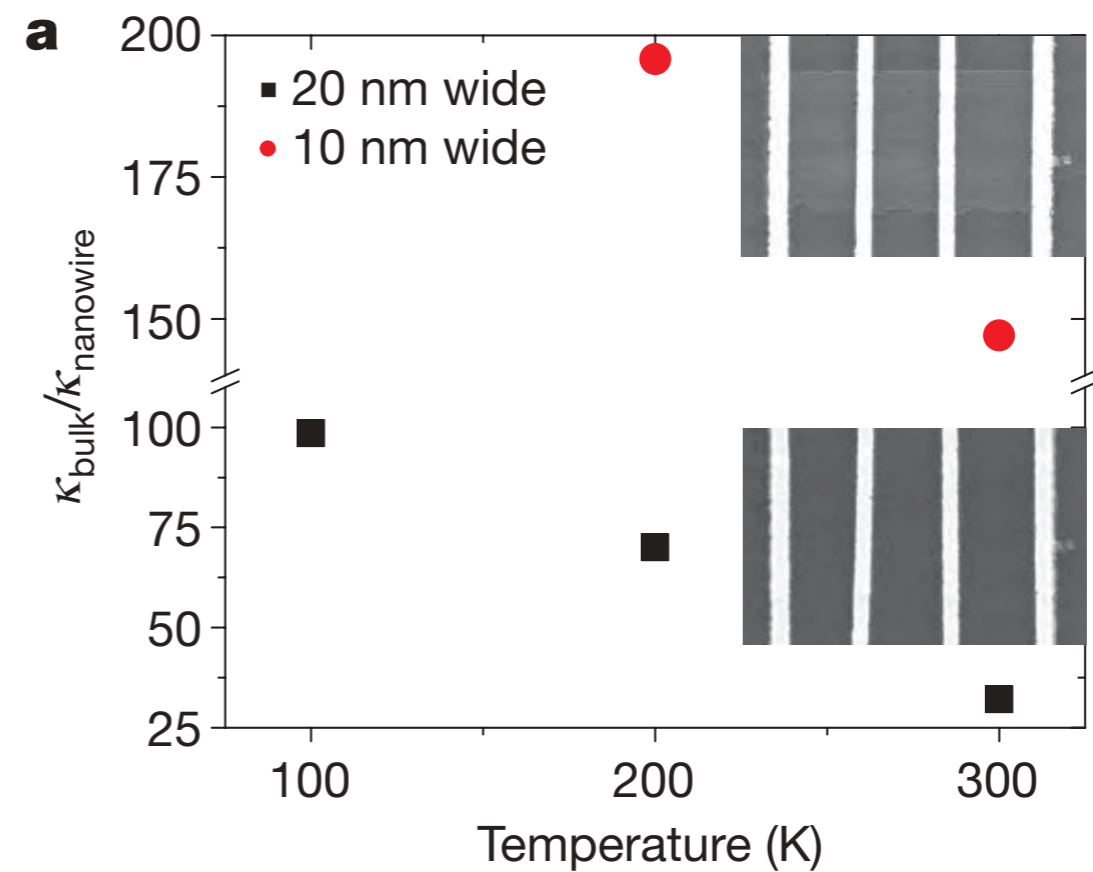
# 1D Nanowires



4 terminal Si nanowires

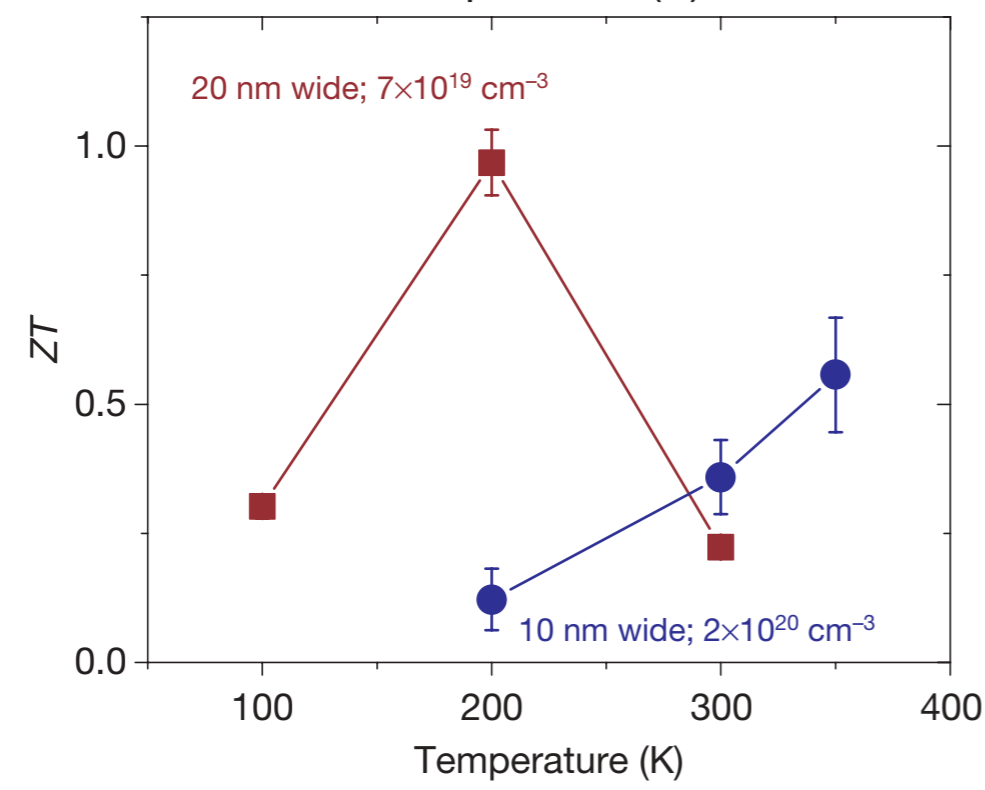
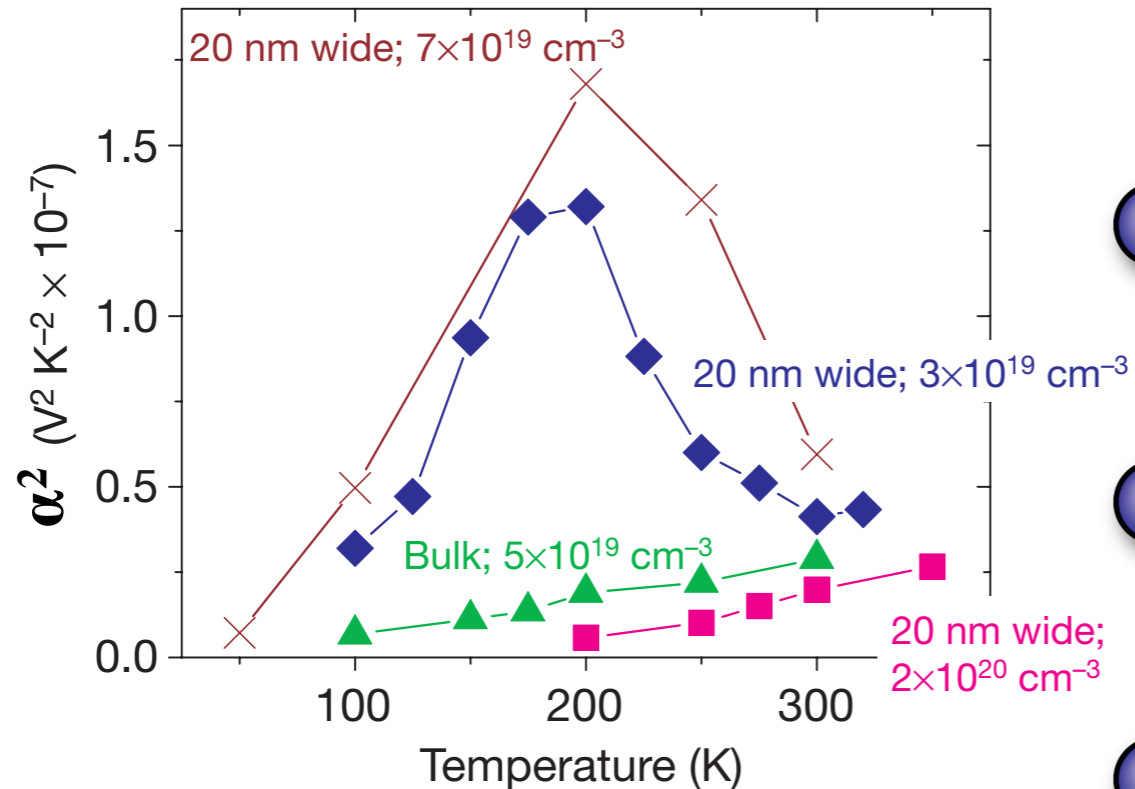
Substrate removed by etching

Heaters



*A.I. Boukai et al., Nature 451, 168 (2007)*

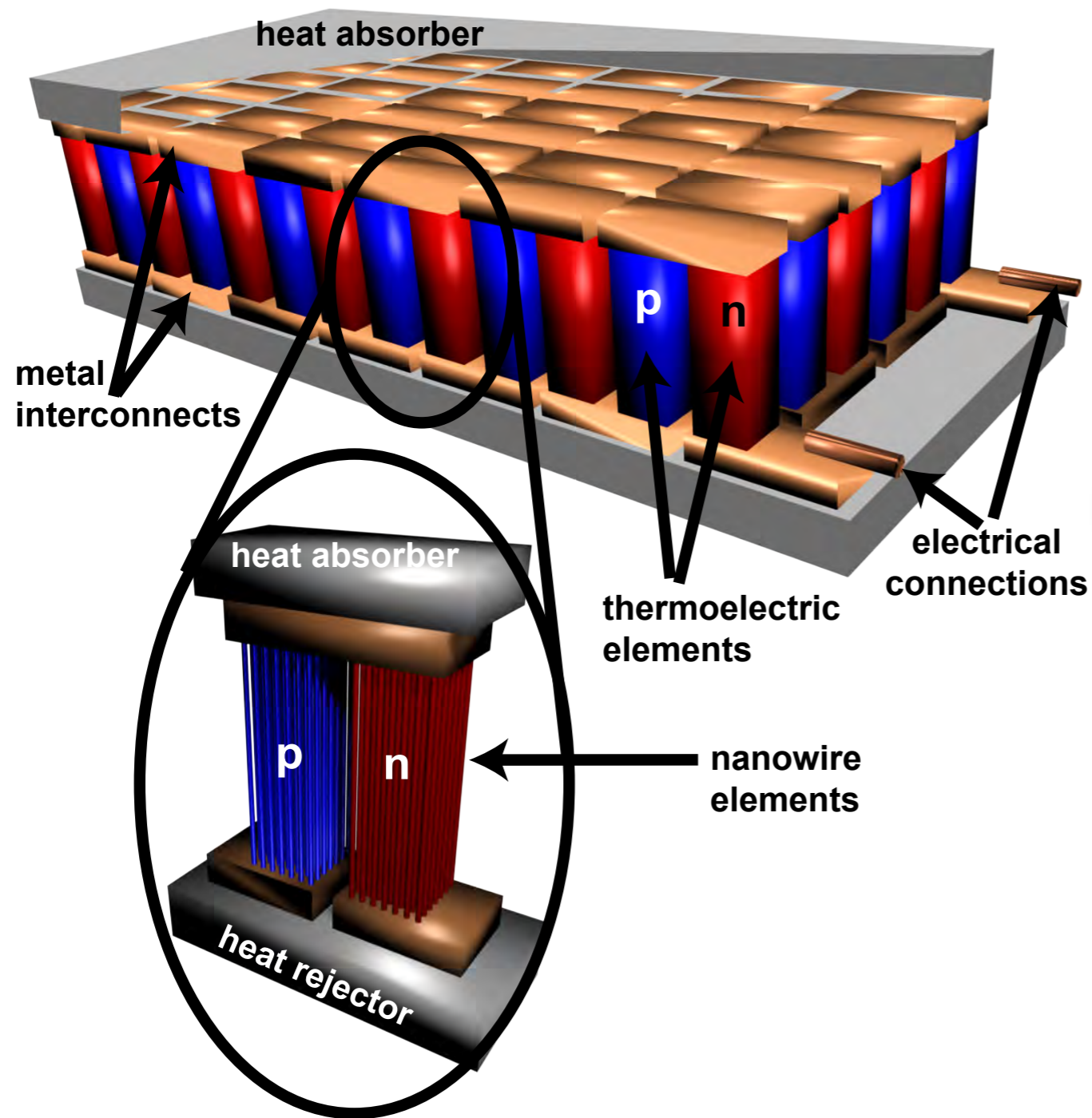
# 1D Silicon Nanowires



- Higher  $\alpha$  from the higher DOS,  $g(E)$
- $\alpha$  increased by  $\sim 2$
- $\kappa$  reduced by factor  $\sim 150$
- ZT increased by factor 600
- Thermal conductivity reduced more than electrical conductivity

*A.I. Boukai et al., Nature 451, 168 (2007)*

# For Module Require Vertical Nanowires



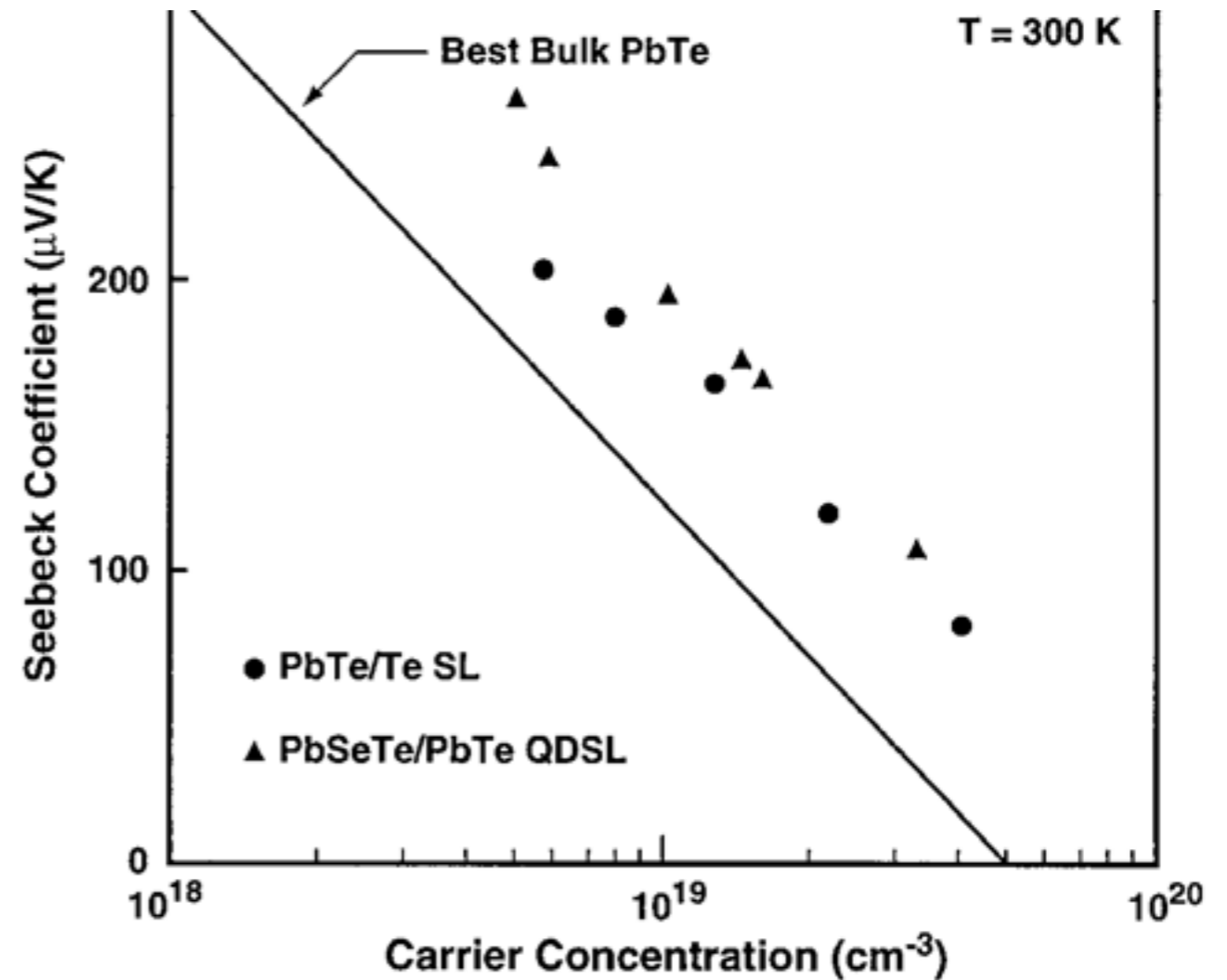
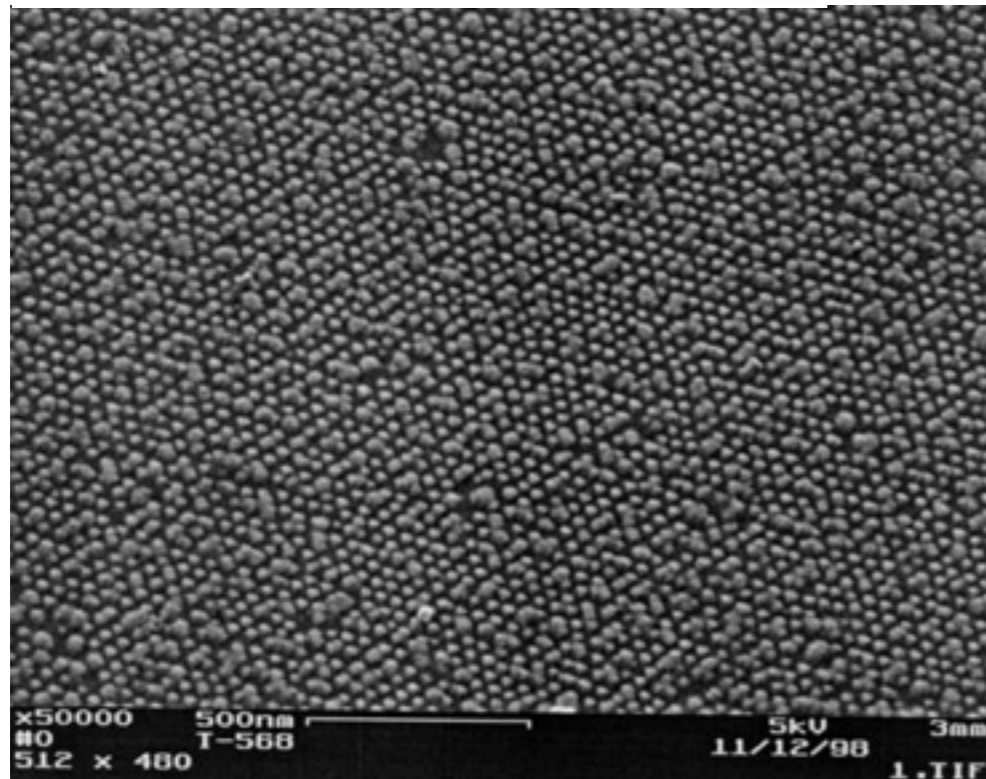
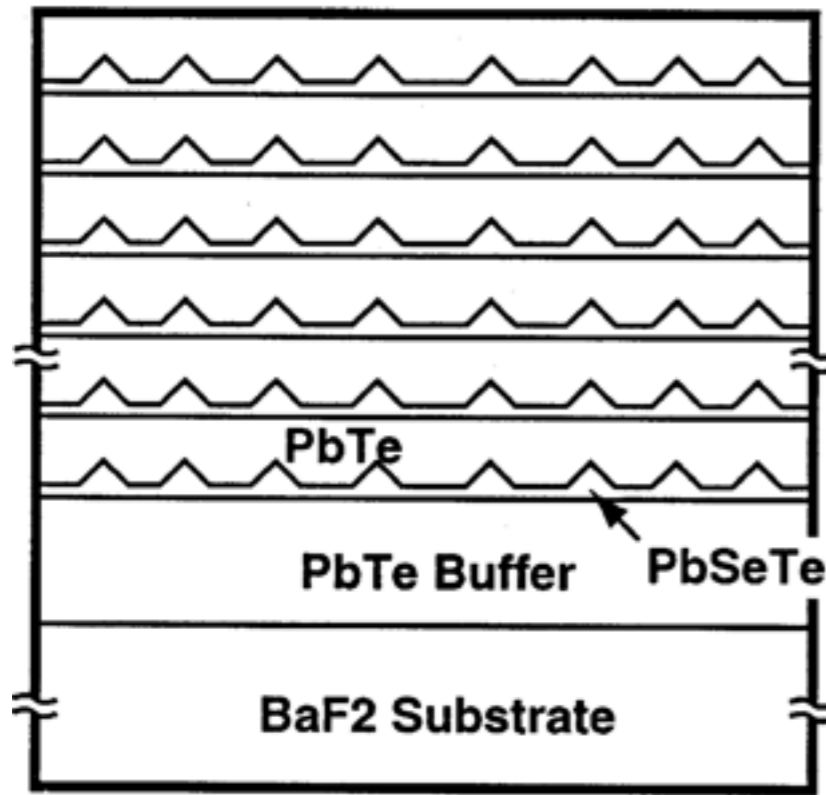
● 20nm vertical Si nanowires  
>> 5  $\mu\text{m}$  height required

● High aspect ratio nanowires  
difficult to etch

● Also difficult to grow



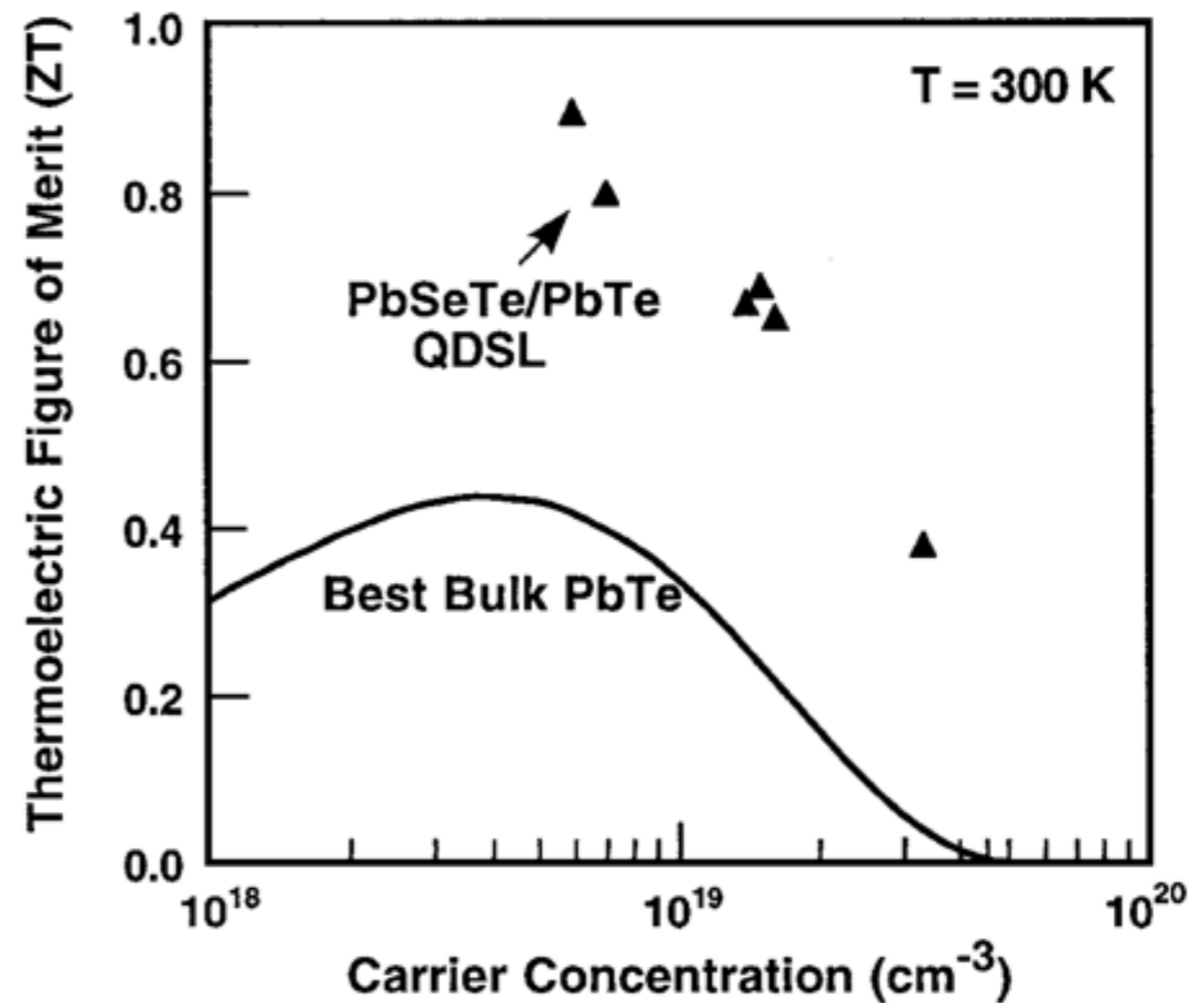
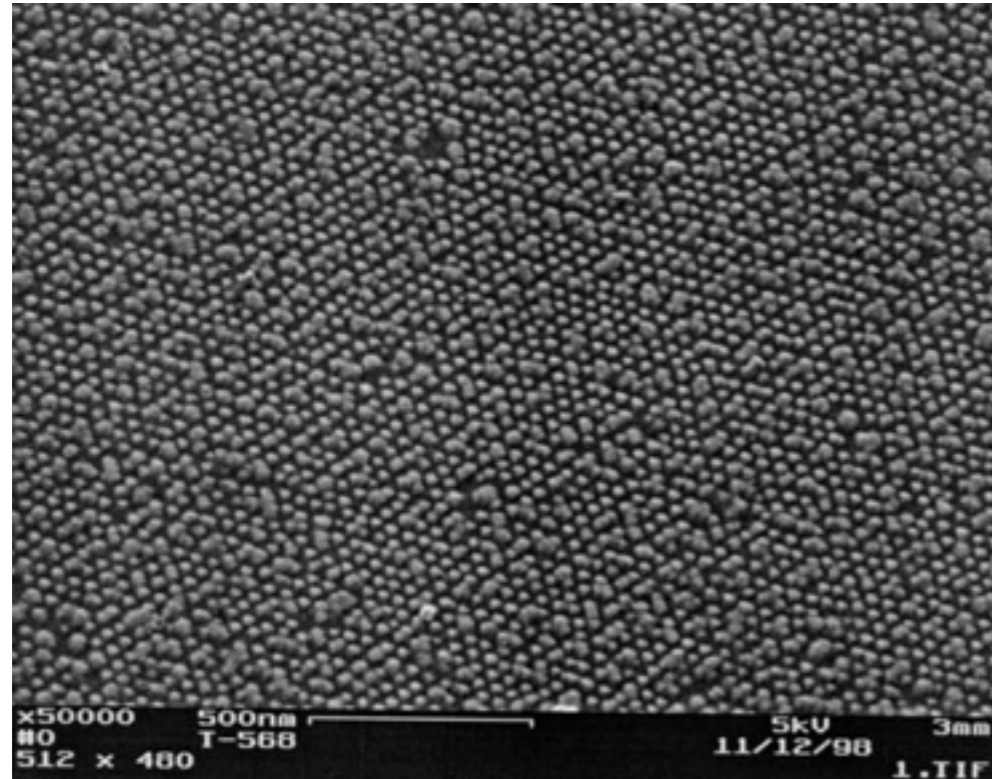
# 0D Quantum Dots



● Seebeck  $\alpha$ : bulk < superlattice < QD

*T.C. Harman et al., J. Elec. Mat. 29, L1 (2000)*

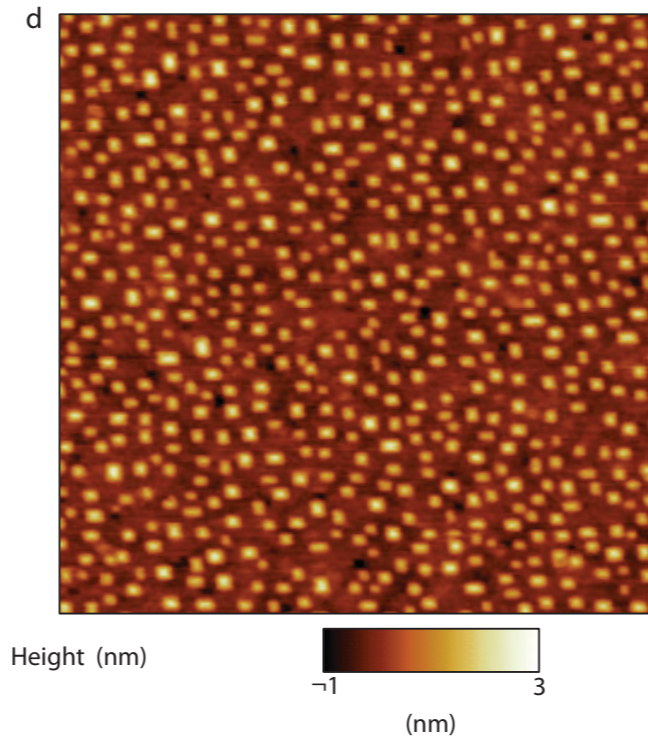
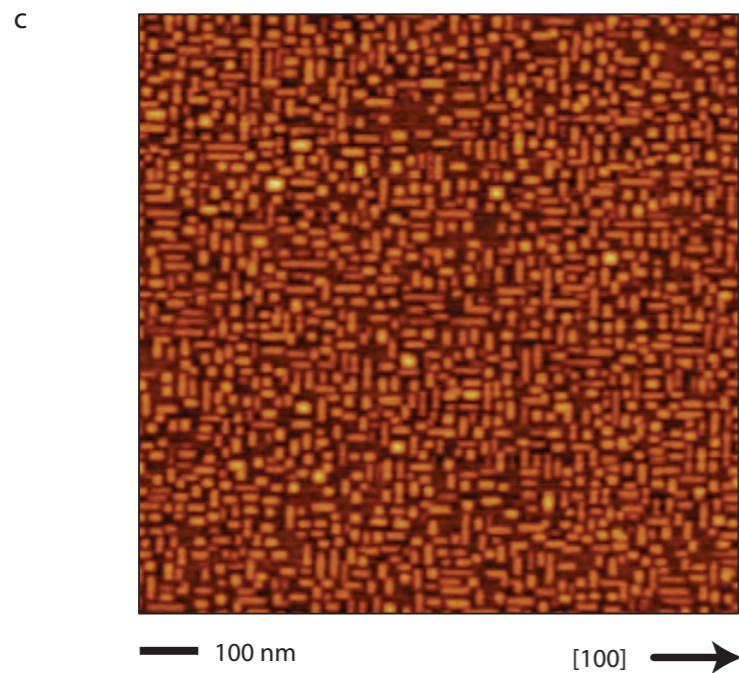
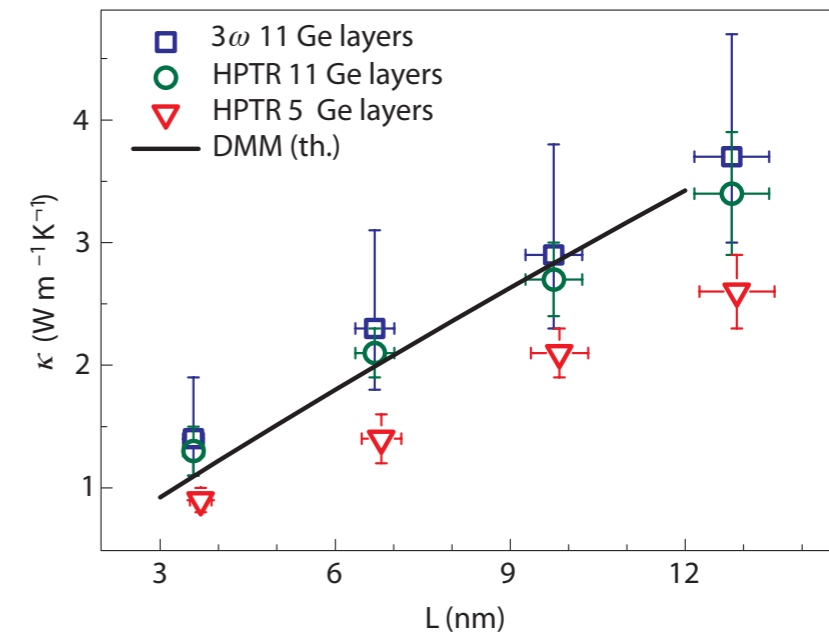
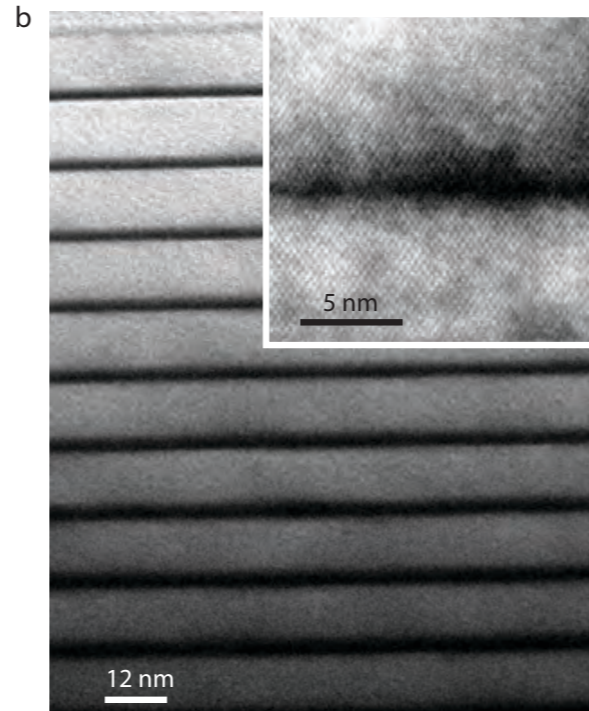
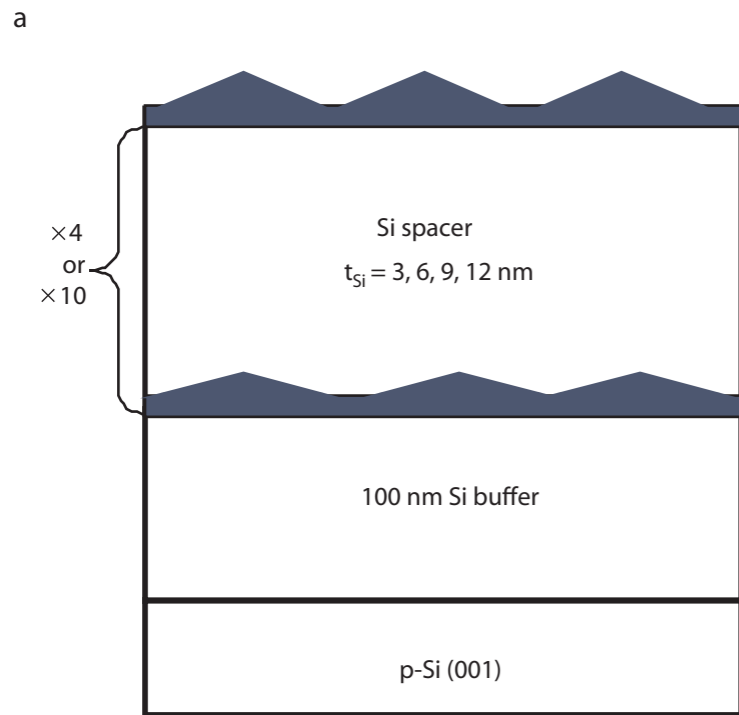
# 0D Quantum Dots



Thermal conductivity reduced more than electrical conductivity

*T.C. Harman et al., J. Elec. Mat. 29, L1 (2000)*

# SiGe Quantum Dots



**Lowest reported  $\kappa$  for SiGe materials but no doping!**

*G. Perot et al., Nat. Mat. 9, 491 (2010)*

# Nanoparticle Engineering

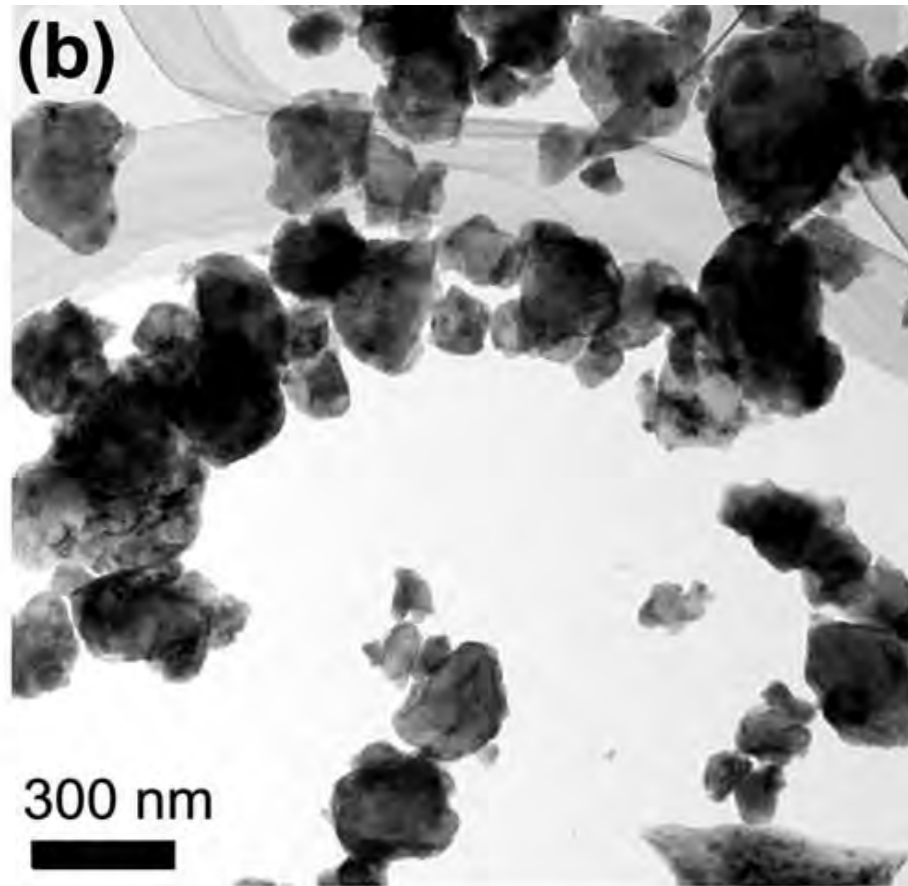
## Advantages:

- Potentially cheap, mass manufacturable technology (hot press)
- Periodic structures not required to reduce thermal conductivity
- In SiGe material, particles below 50 nm demonstrate improved ZT

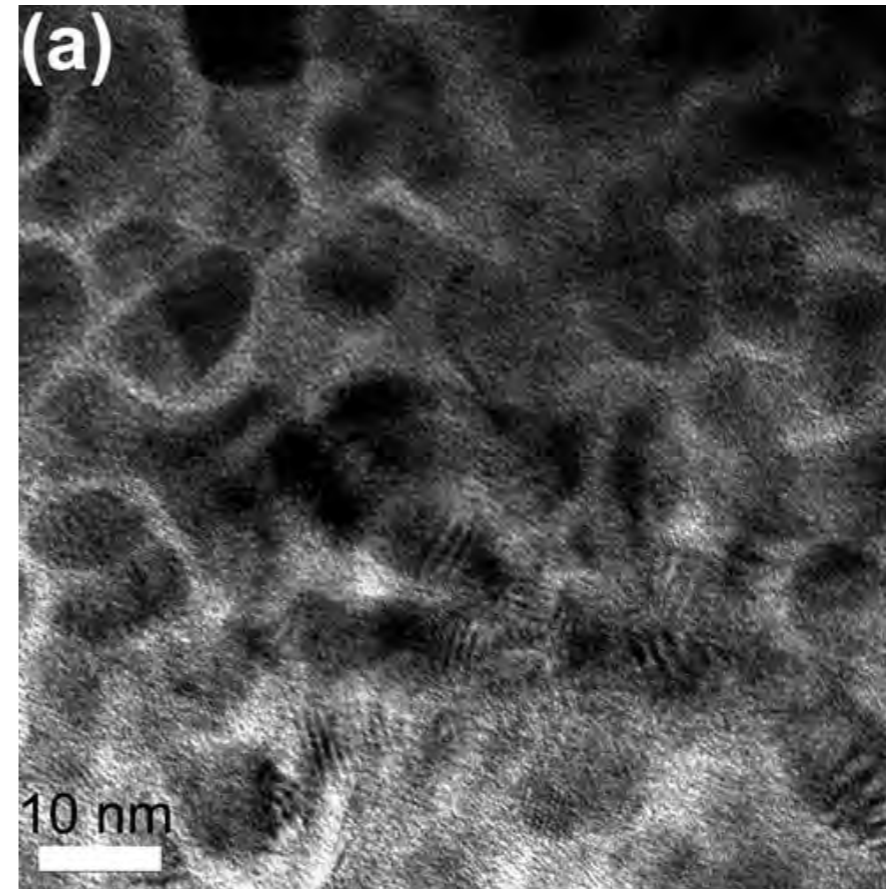
## Disadvantages:

- Many orders of magnitude change in ZT for small change in density (few %) → voids in material
- Technology immature and process dependent

# Nanoparticle / Quantum Dot Materials

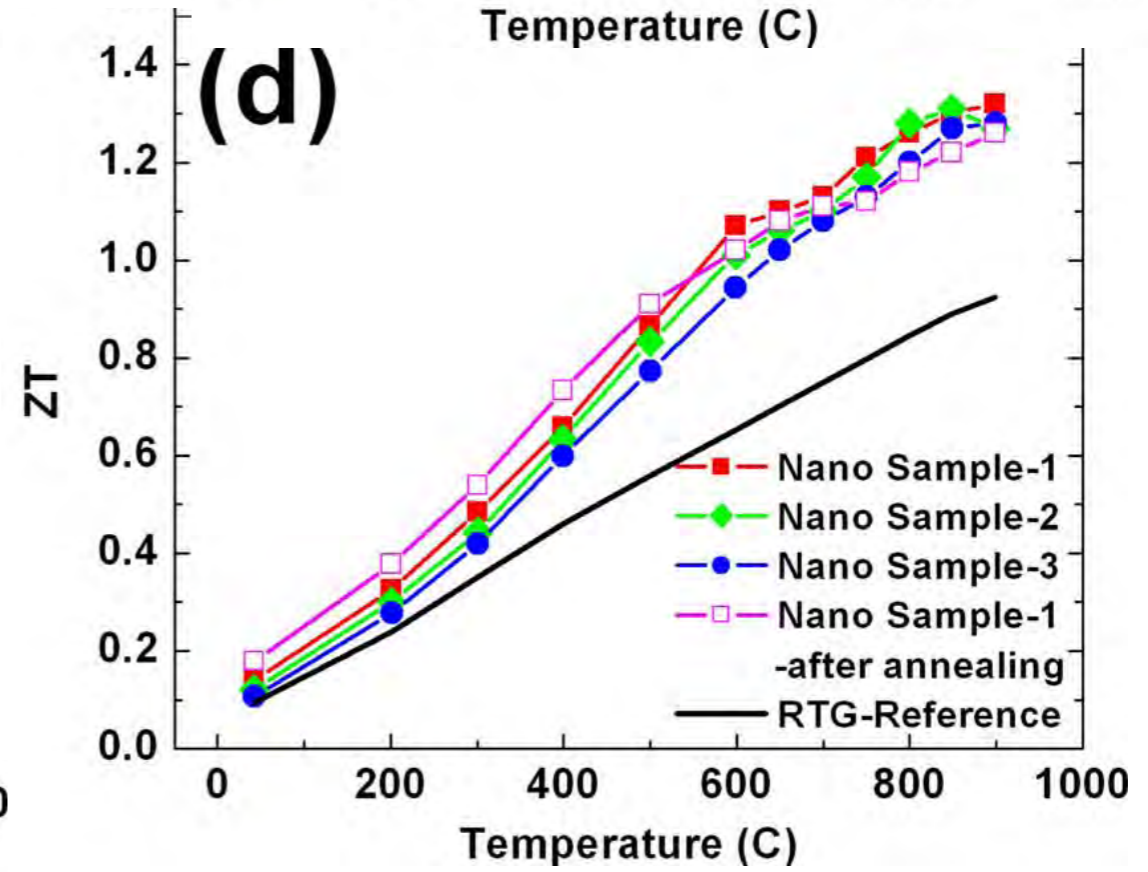
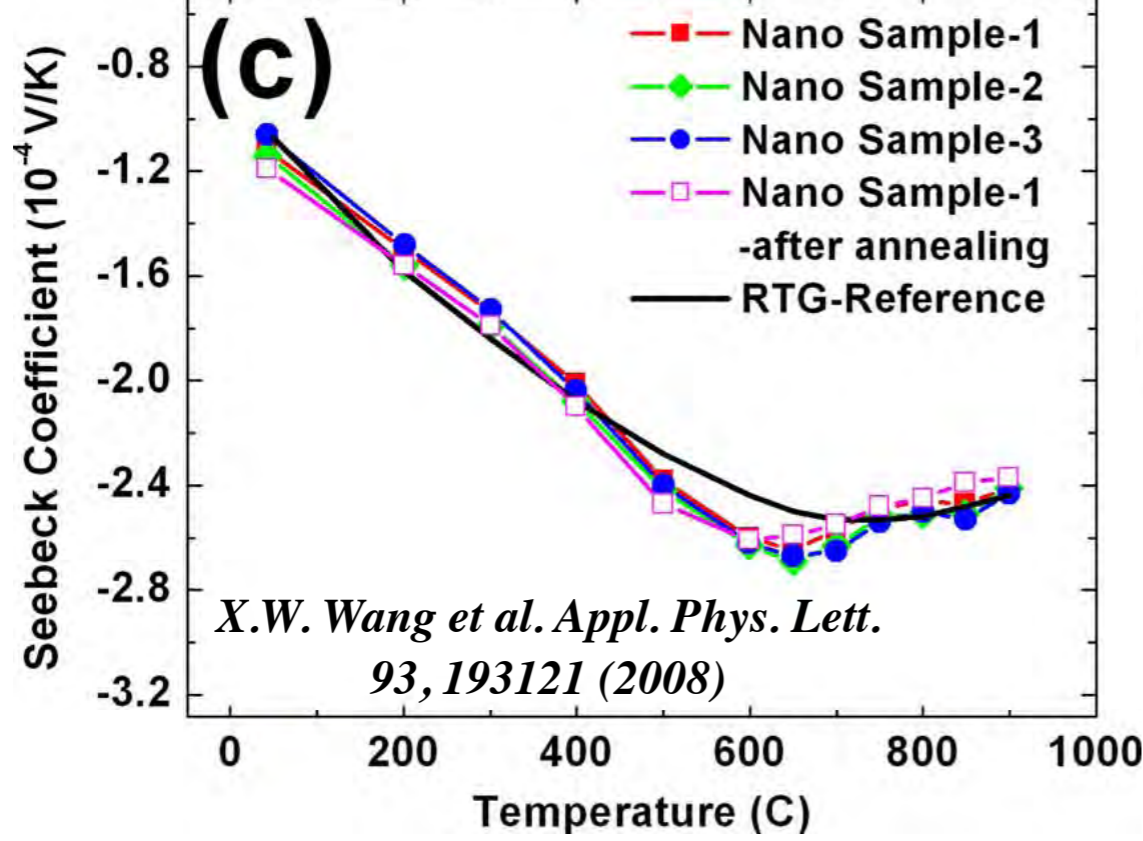
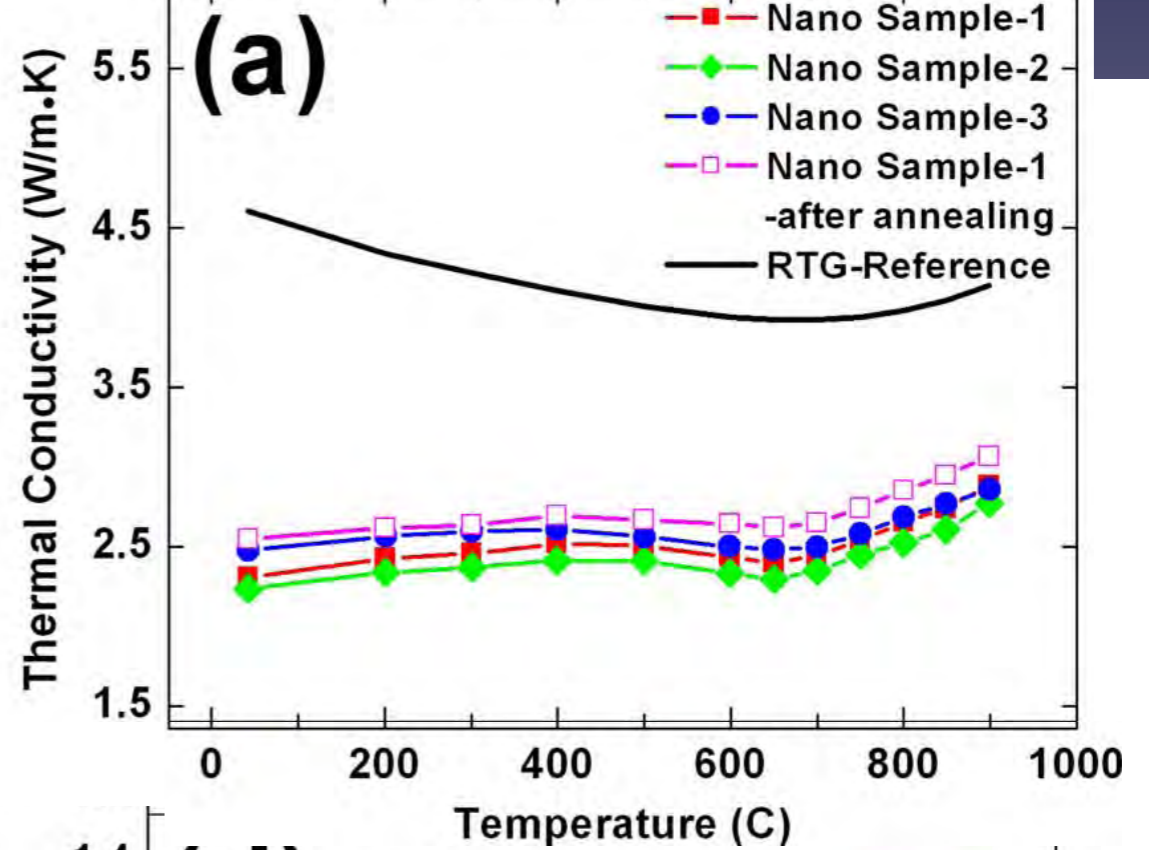
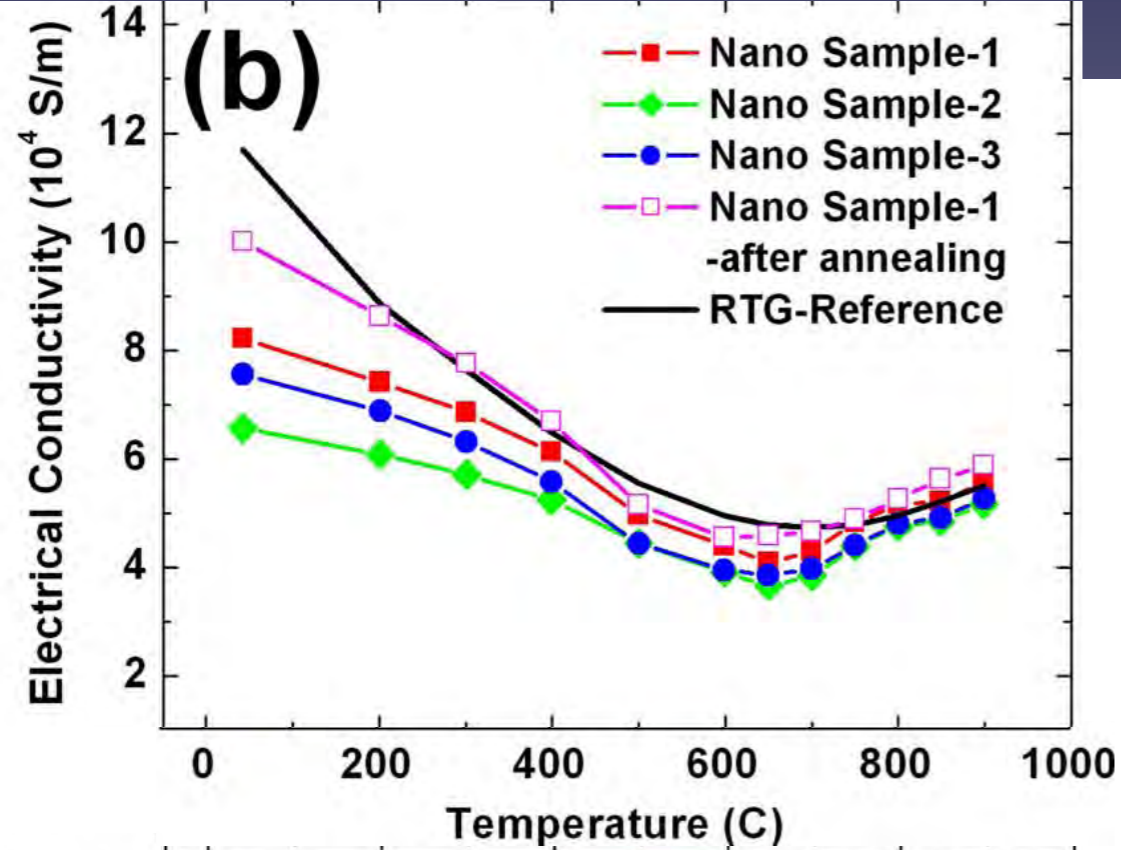


**Ball milled bulk SiGe alloy**



**Hot pressed material with ~ 10 nm nanoparticles**

*X.W. Wang et al. Appl. Phys. Lett. 93, 193121 (2008)*



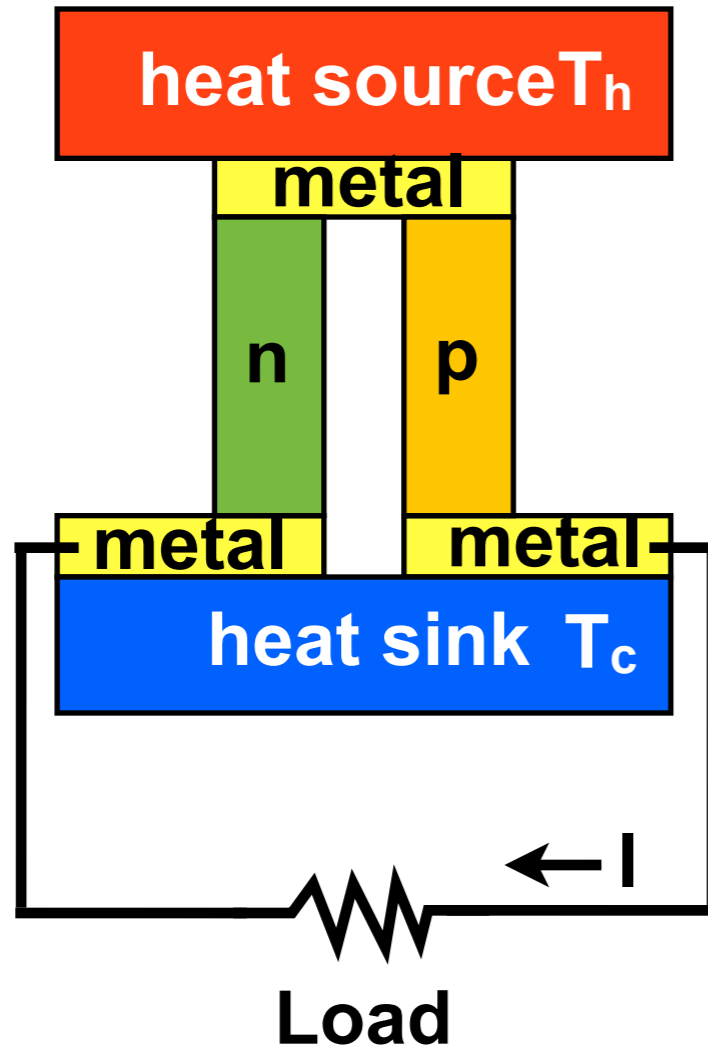
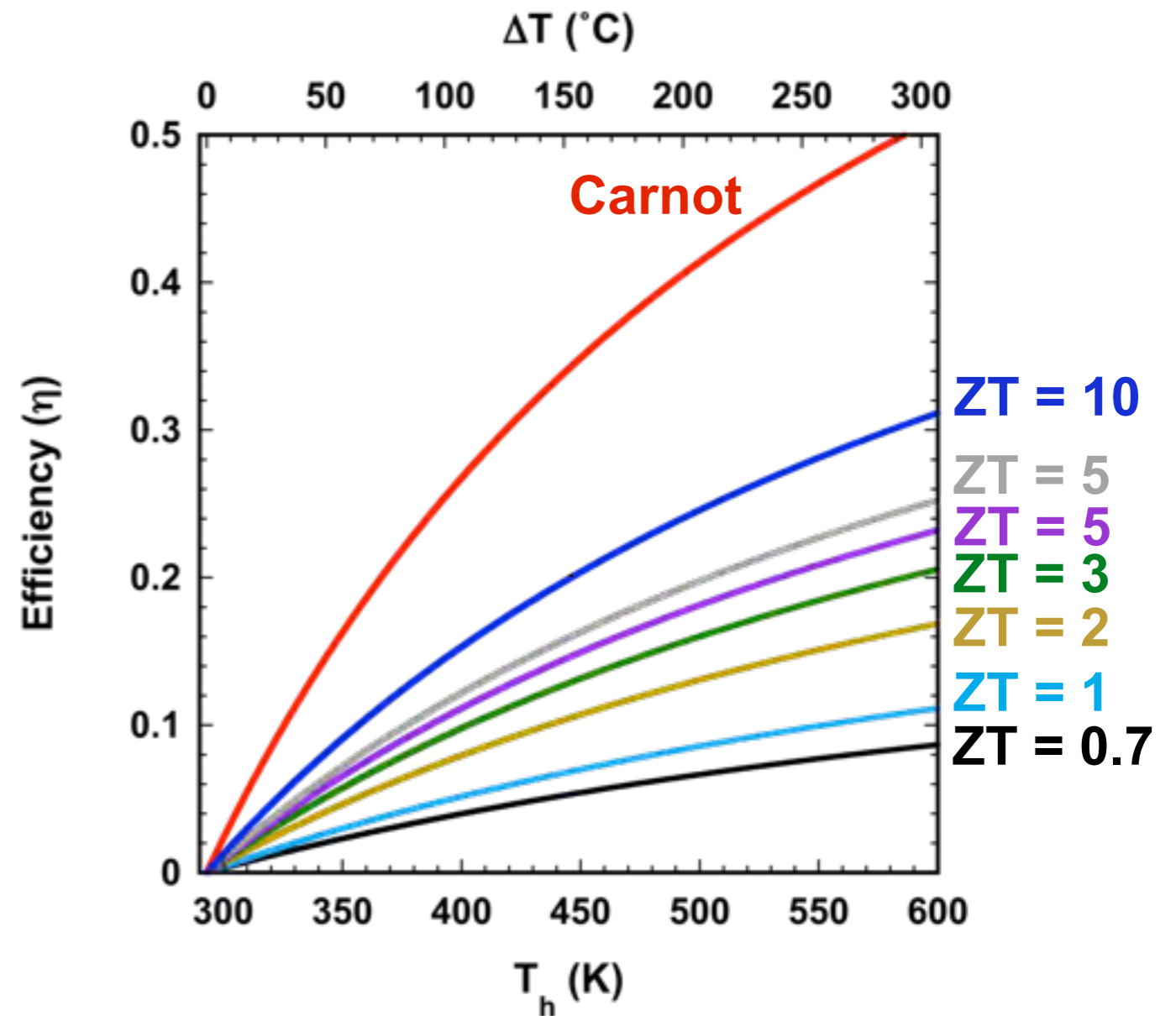


Figure of merit

$$ZT = \frac{\alpha^2 \sigma}{\kappa} T$$

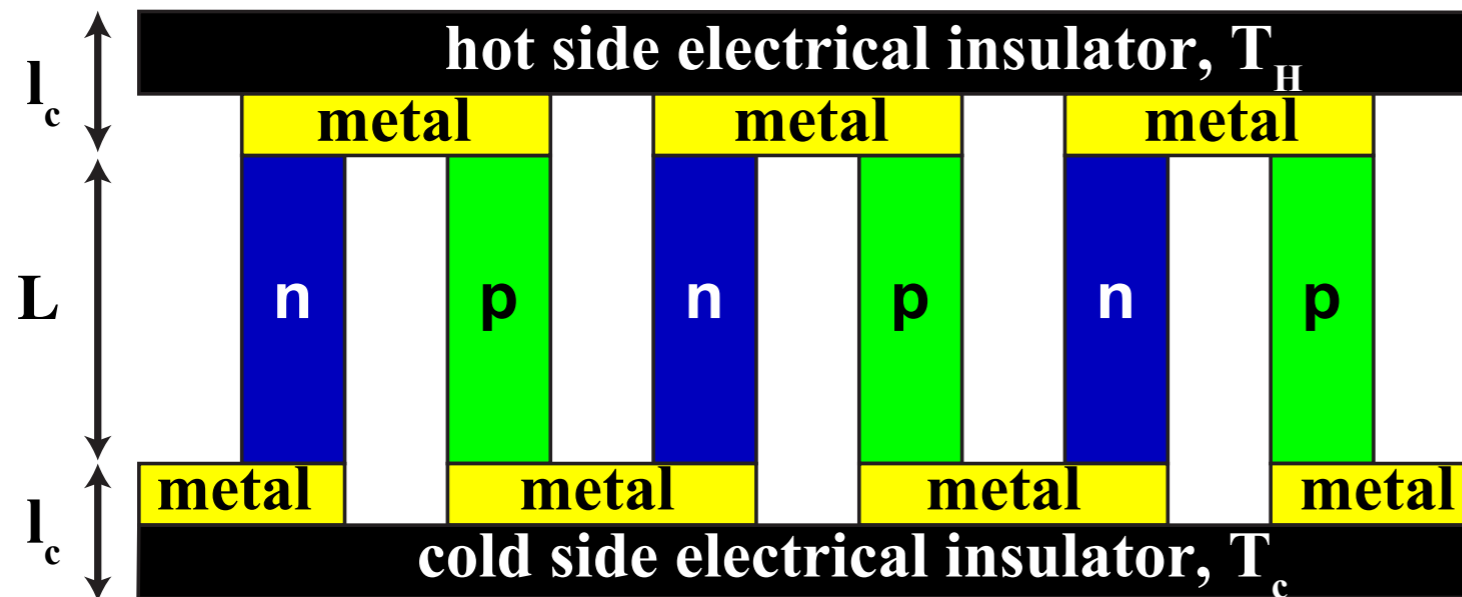
Power factor =  $\alpha^2 \sigma$

$$\eta = \frac{\Delta T}{T_h} \frac{\sqrt{1 + ZT} - 1}{\sqrt{1 + ZT} + \frac{T_c}{T_h}}$$



Impedance matching and maximum power point tracking are key for thermoelectrics

# Voltage / Current from Real Thermoelectric Modules



$A$  = module leg area

$L$  = module leg length

$N$  = number of modules

$\kappa_c$  = thermal contact conductivity

$\rho_c$  = electrical contact resistivity

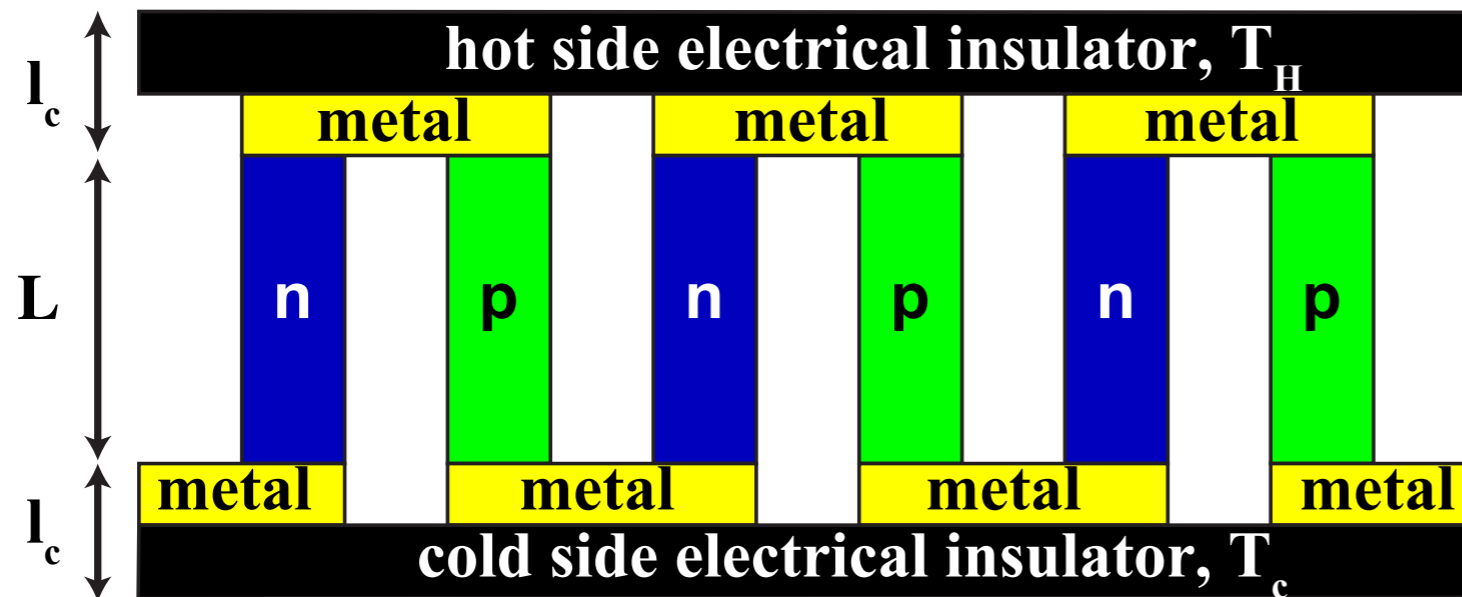
$$V = \frac{N\alpha\Delta T}{1 + 2\frac{\kappa l_c}{\kappa_c L}}$$

$$I = \frac{A\alpha\sigma\Delta T}{2(\rho_c\sigma + L)\left(1 + 2\frac{\kappa l_c}{\kappa_c L}\right)}$$

*D.M. Rowe (Ed.), 'Thermoelectrics Handbook: Macro to Nano' CRC Taylor and Francis (2006)*



# Power from Real Thermoelectric Modules



$A$  = module leg area

$L$  = module leg length

$N$  = number of modules

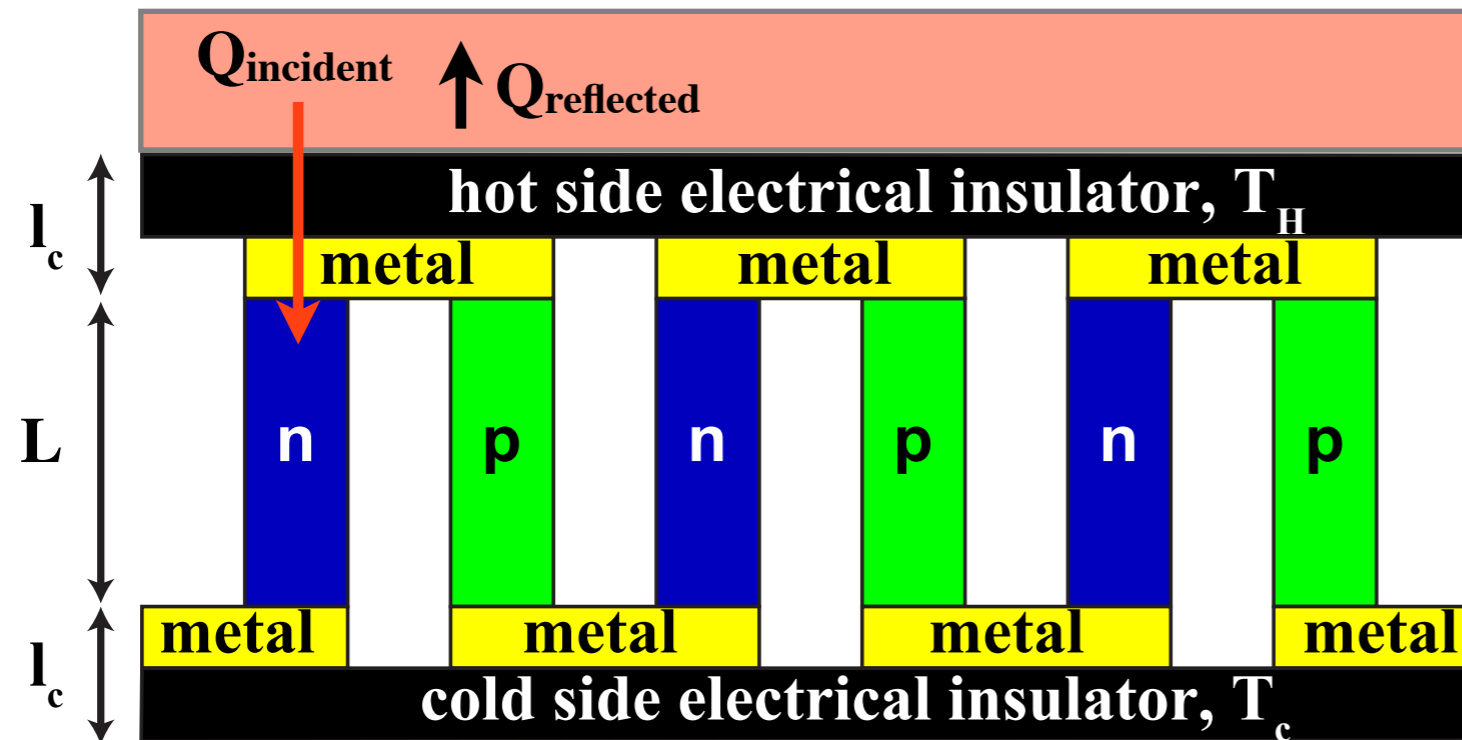
$\kappa_c$  = thermal contact conductivity

$\rho_c$  = electrical contact resistivity

$$P = \frac{\alpha^2 \sigma AN \Delta T^2}{2(\rho_c \sigma + L) \left(1 + 2 \frac{\kappa l_c}{\kappa_c L}\right)}$$

*D.M. Rowe (Ed.), 'Thermoelectrics Handbook: Macro to Nano' CRC Taylor and Francis (2006)*

# Maximum Output Power



$A$  = module leg area

$L$  = module leg length

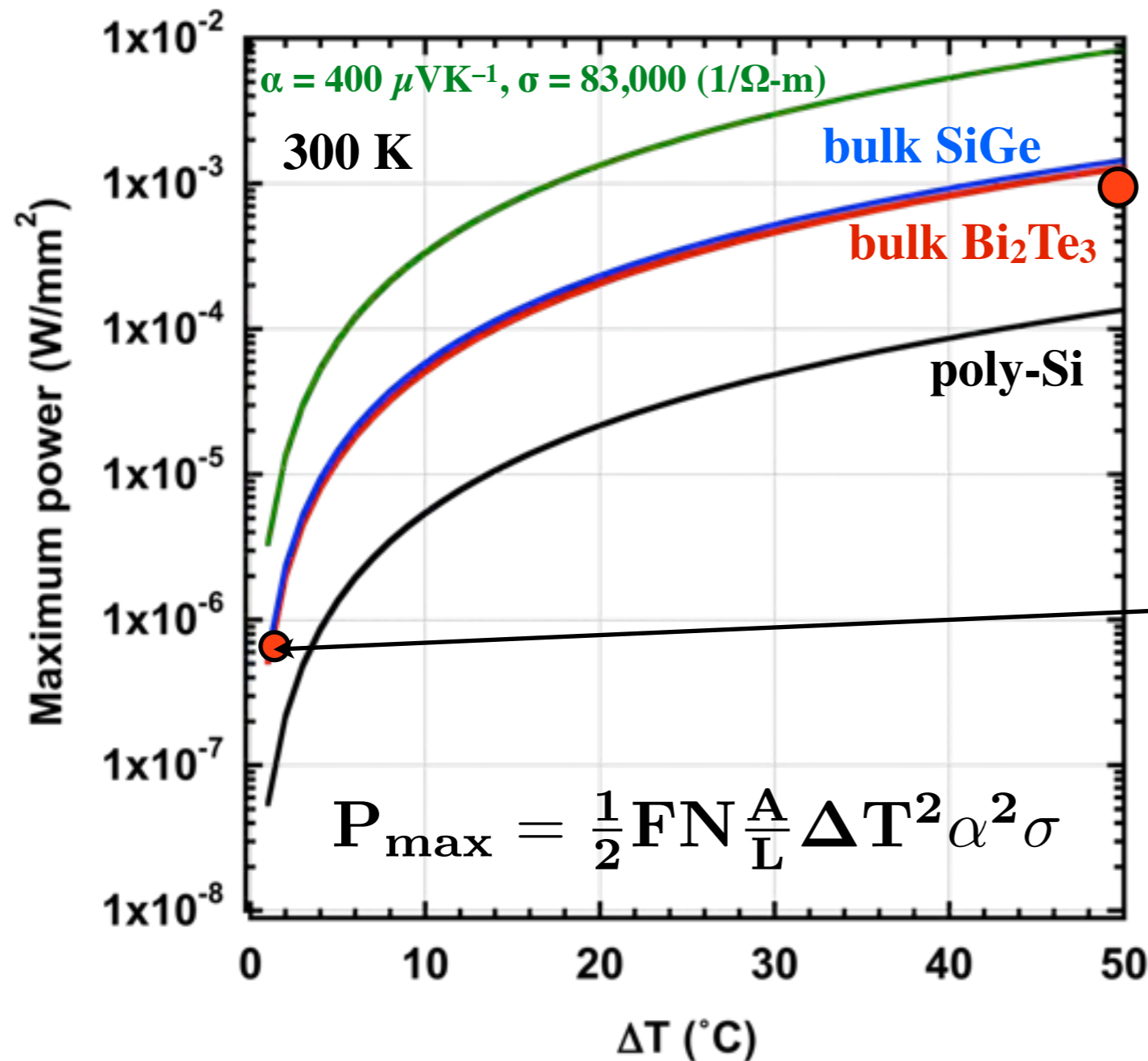
$N$  = number of modules

- $F$  = fabrication factor = perfect system –  $R_{\text{contact}}$  –  $R_{\text{series}}$  – Lost heat
- **Practical systems: both electrical and thermal impedance matching is required**

$$P_{\text{max}} = \frac{1}{2} F N \frac{A}{L} \Delta T^2 \alpha^2 \sigma$$

*D.M. Rowe (Ed.), 'Thermoelectrics Handbook: Macro to Nano' CRC Taylor and Francis (2006)*

# Maximum Power Examples



Dense microfabricated module

$N = 2500$

$L = 10 \mu\text{m}$

$l_c = 1 \mu\text{m}$

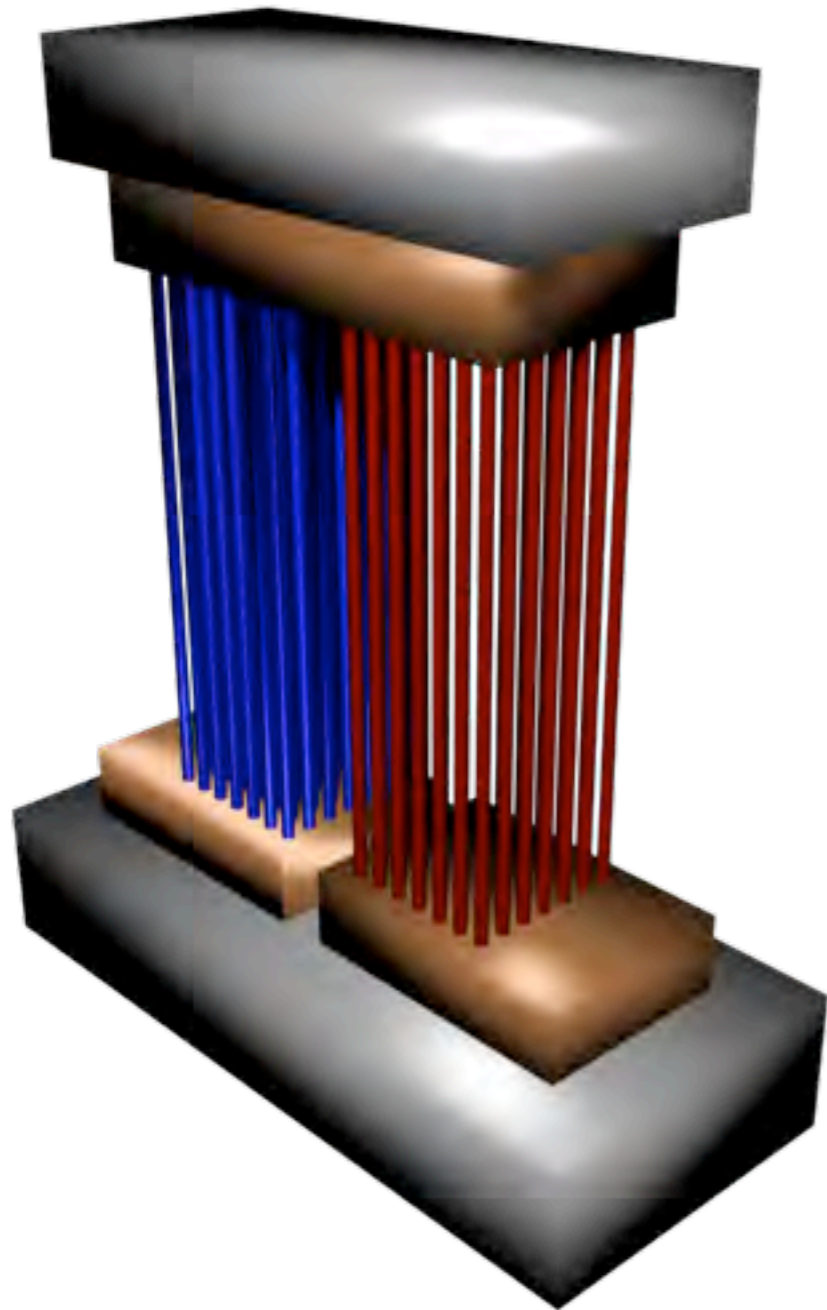
$A = 10 \times 10 \mu\text{m}^2$

$F = 0.2$

bulk  $\text{Bi}_2\text{Te}_3$  experiment  
 Nat. Mat. 2, 528 (2003)  
 (scaled from  $L = 20 \rightarrow 10 \mu\text{m}$ )

N.B. The thermal conductivity must also be considered for  $\Delta T_{\max}$ !

# Generate Renewable Energy Efficiently using Nanofabricated Silicon (GREEN Silicon)



**D.J. Paul, J.M.R. Weaver, P. Dobson & J. Watling**  
University of Glasgow, U.K.

**G. Isella, D. Chrastina & H. von Känel**  
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**J. Stangl, T. Fromherz & G. Bauer**  
University of Linz, Austria

**E. Müller**  
ETH Zürich, Switzerland

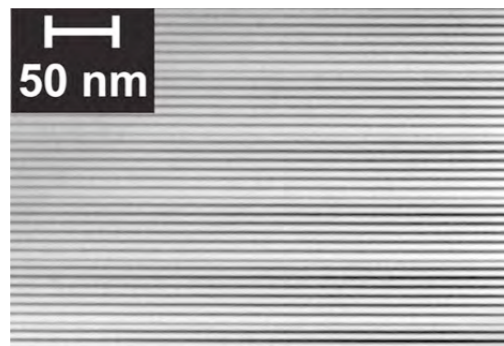
**D.J. Paul – Co-ordinator GREEN Si**  
**EC FP7 ICT FET**  
**"2ZeroPowerICT" No.: 257750**



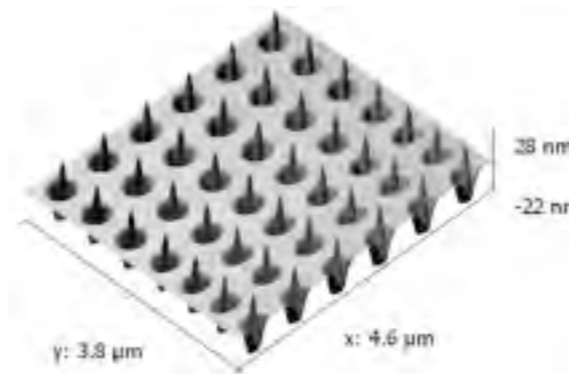
**University  
of Glasgow**

# GREEN Silicon Approach

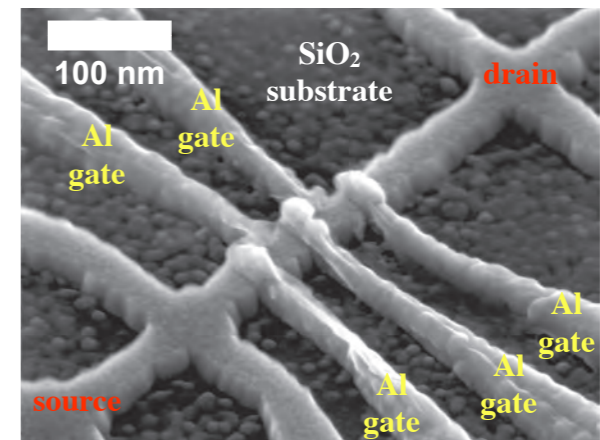
Low dimension technology



superlattice

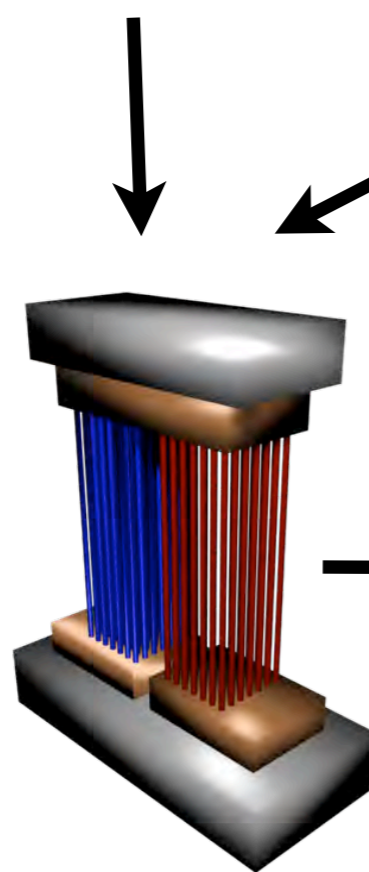


quantum dot

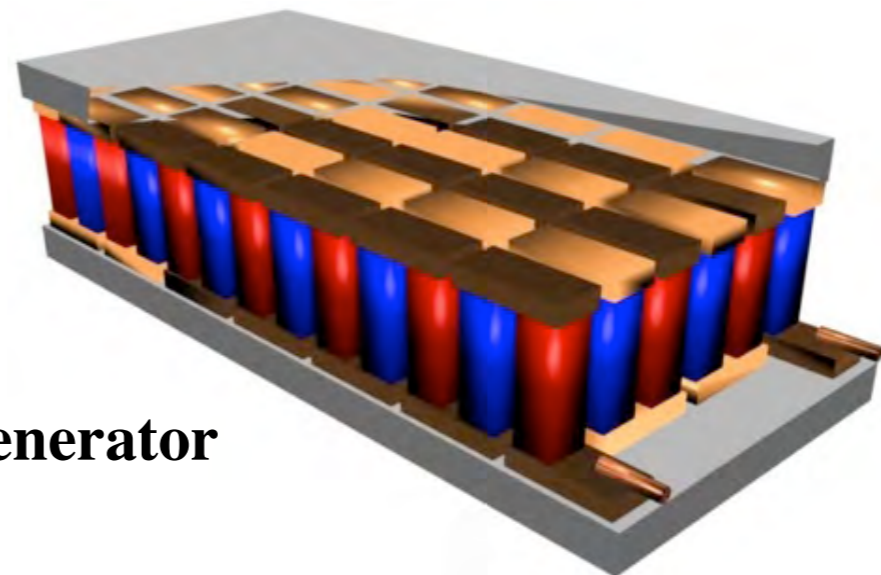


nanowires

Module



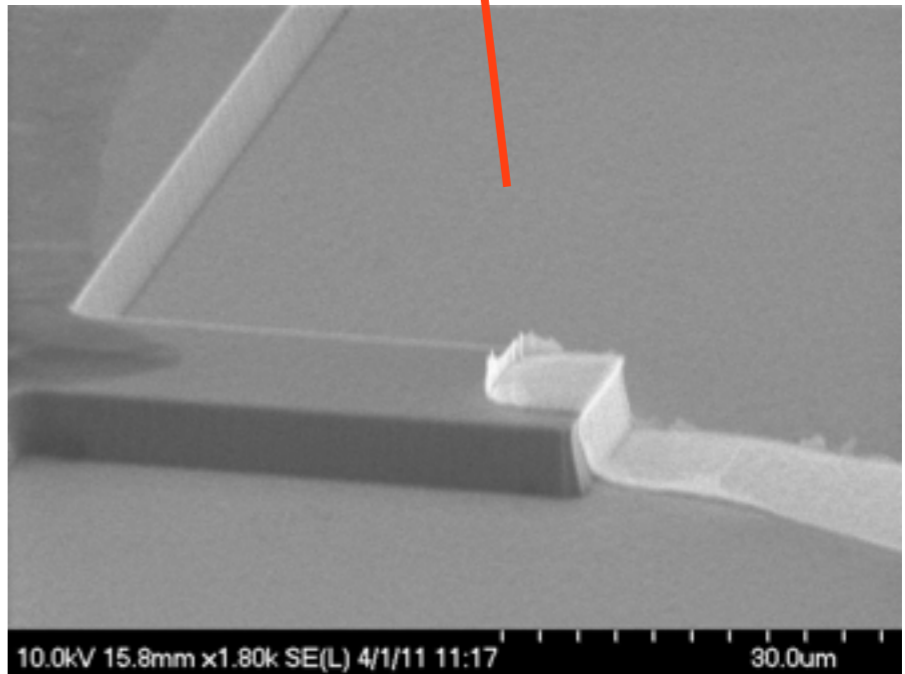
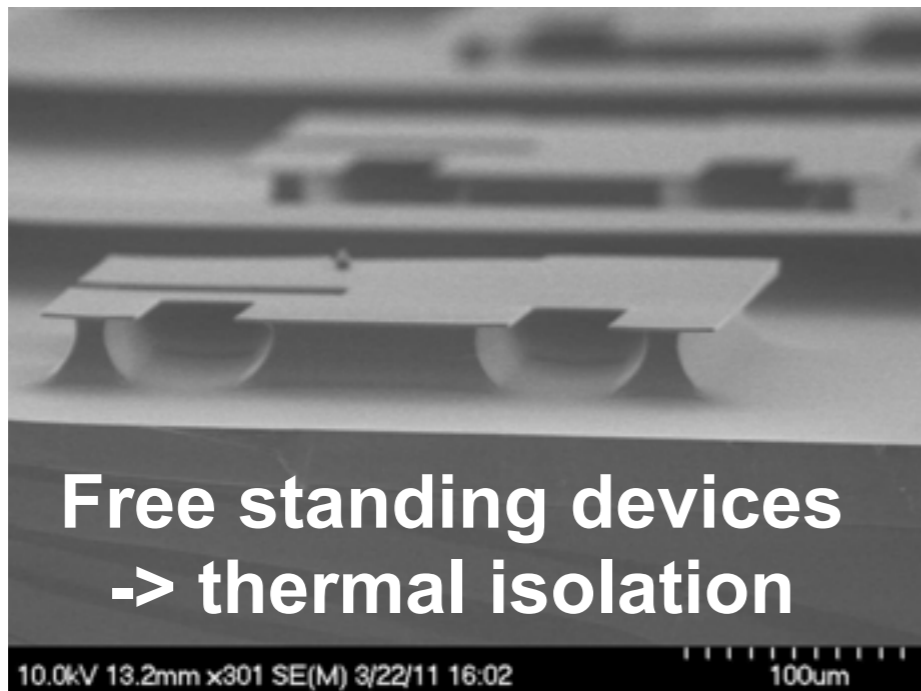
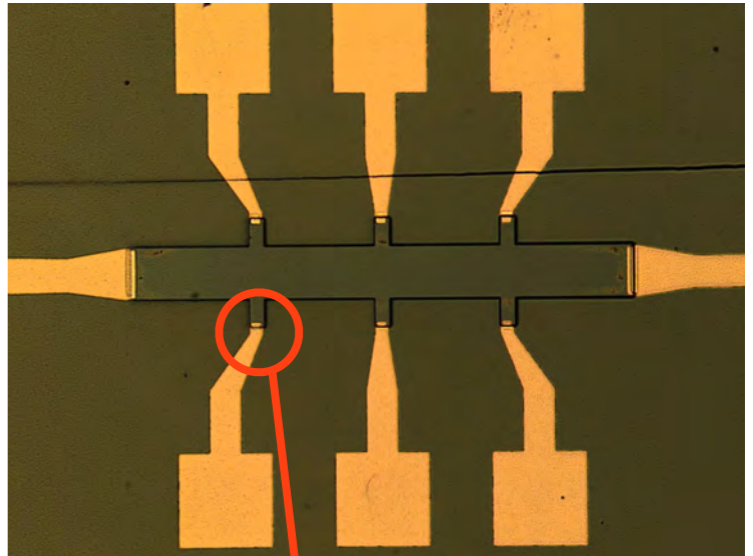
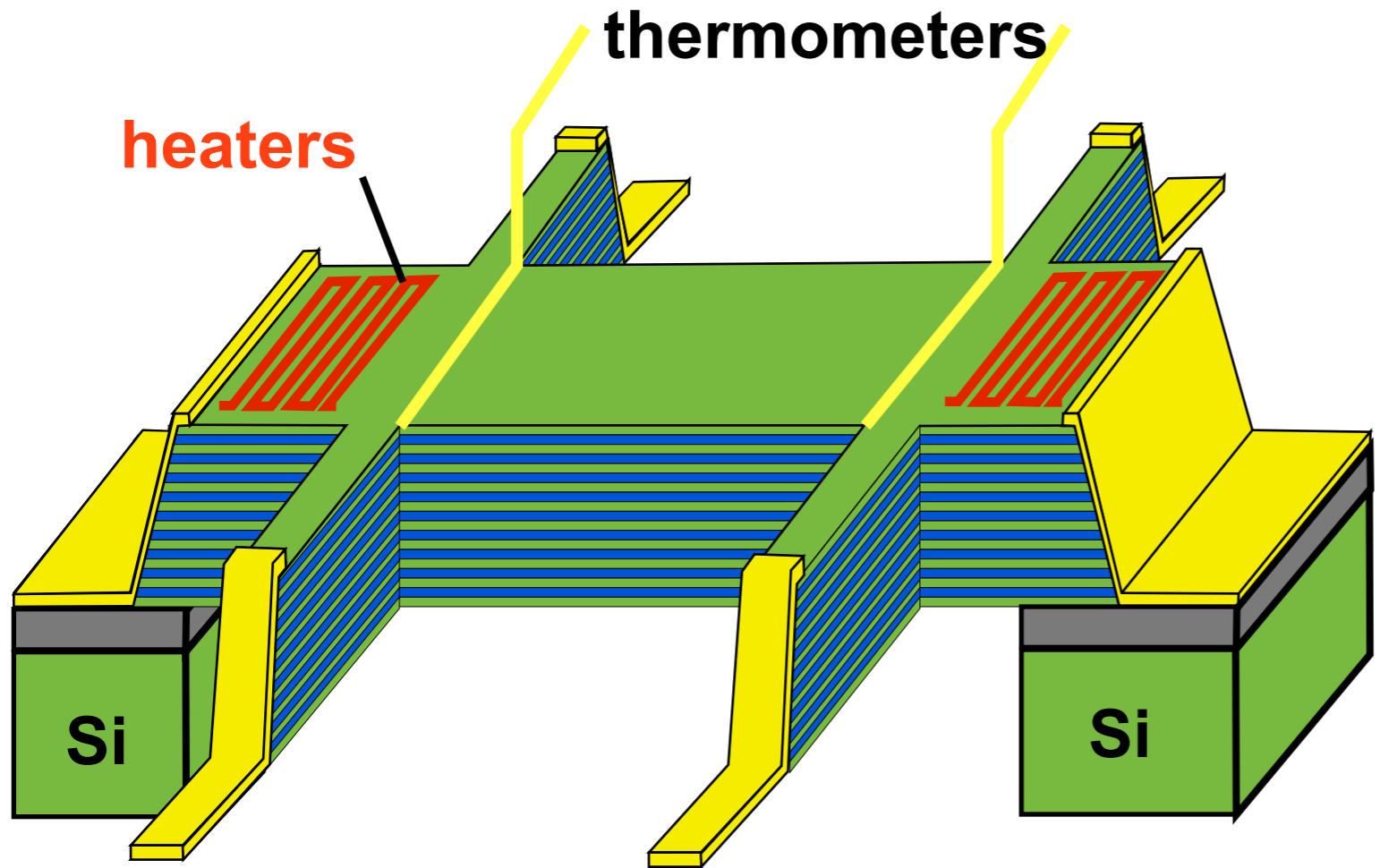
Generator



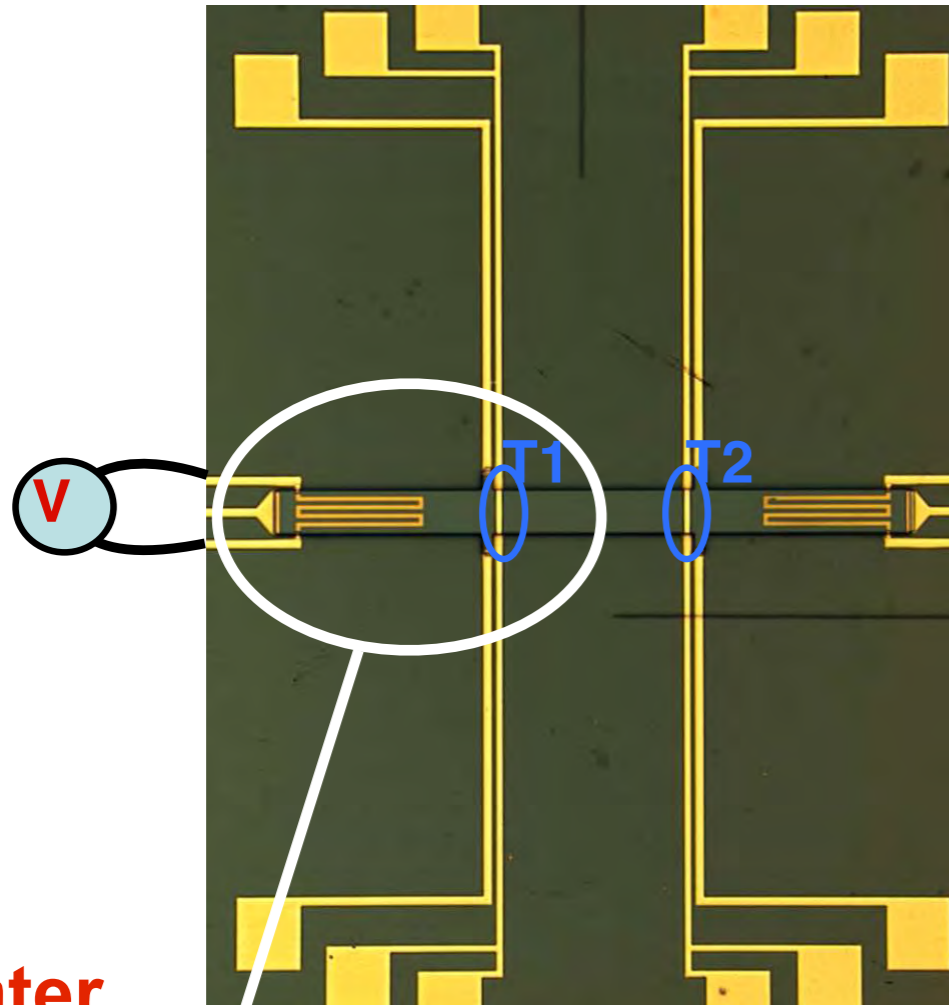
D.J. Paul – Co-ordinator GREEN Si  
 EC FP7 ICT FET  
 "2ZeroPowerICT" No.: 257750



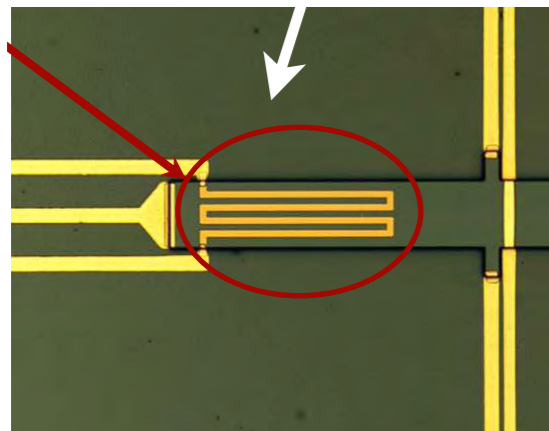
University of Glasgow

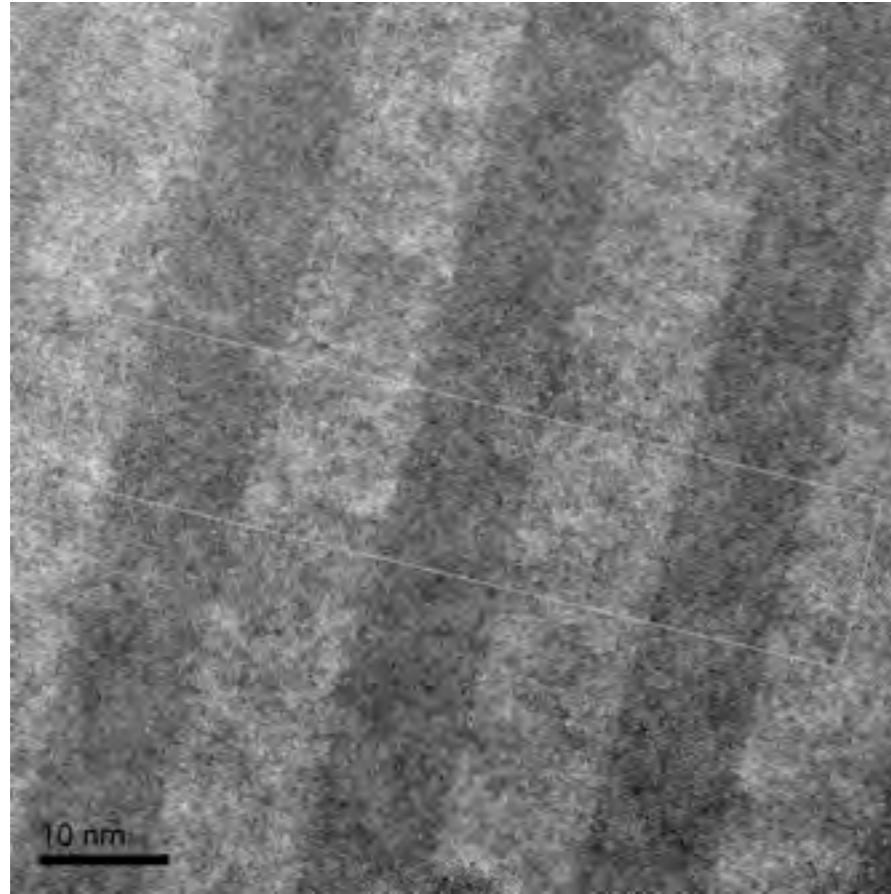


Substrate removed

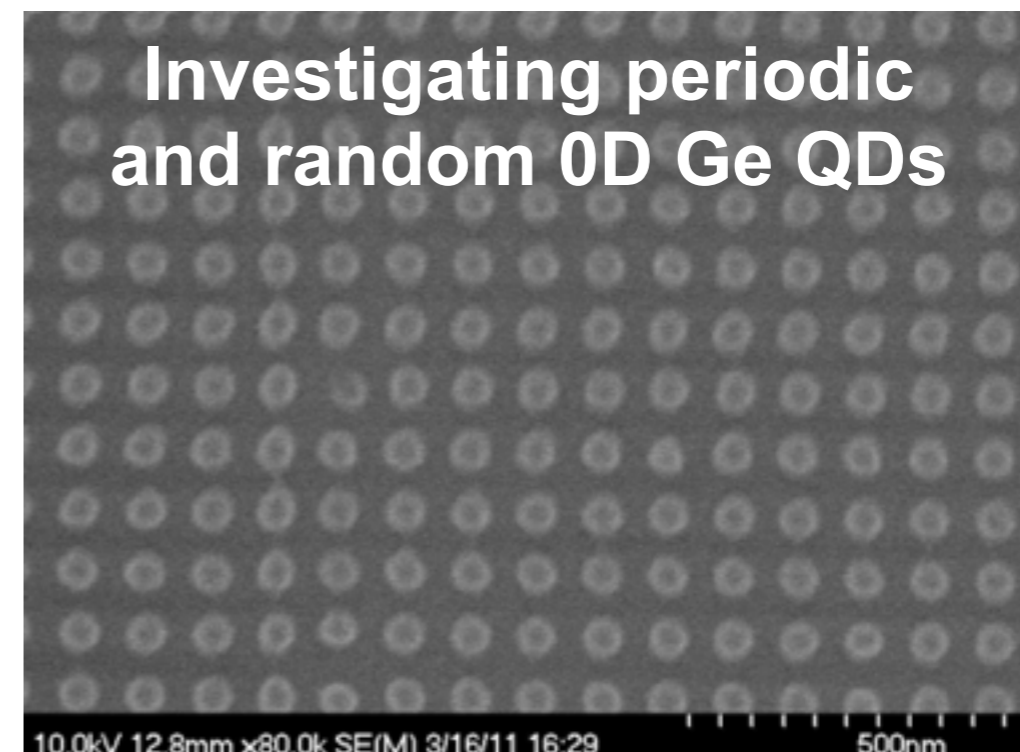
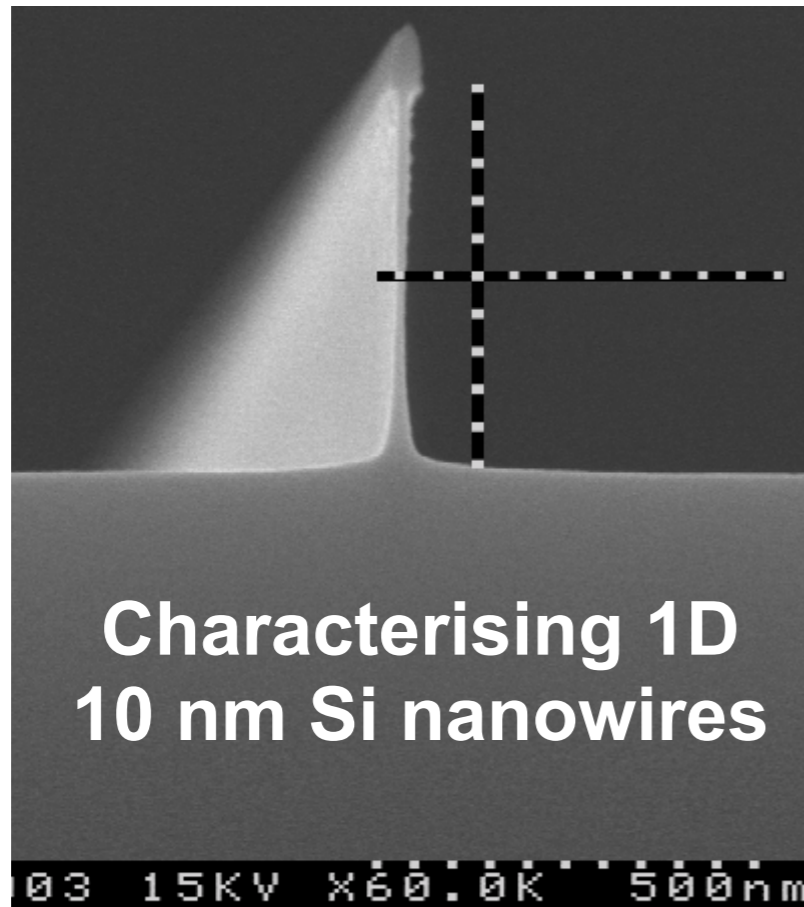
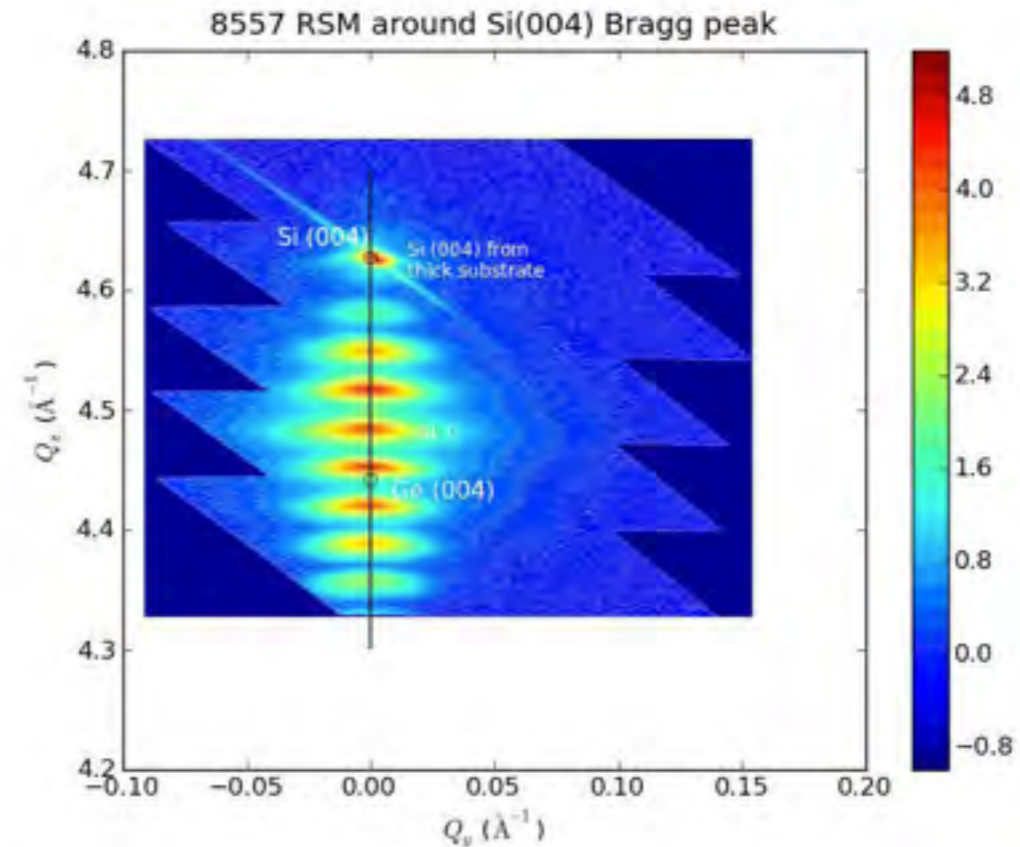


heater



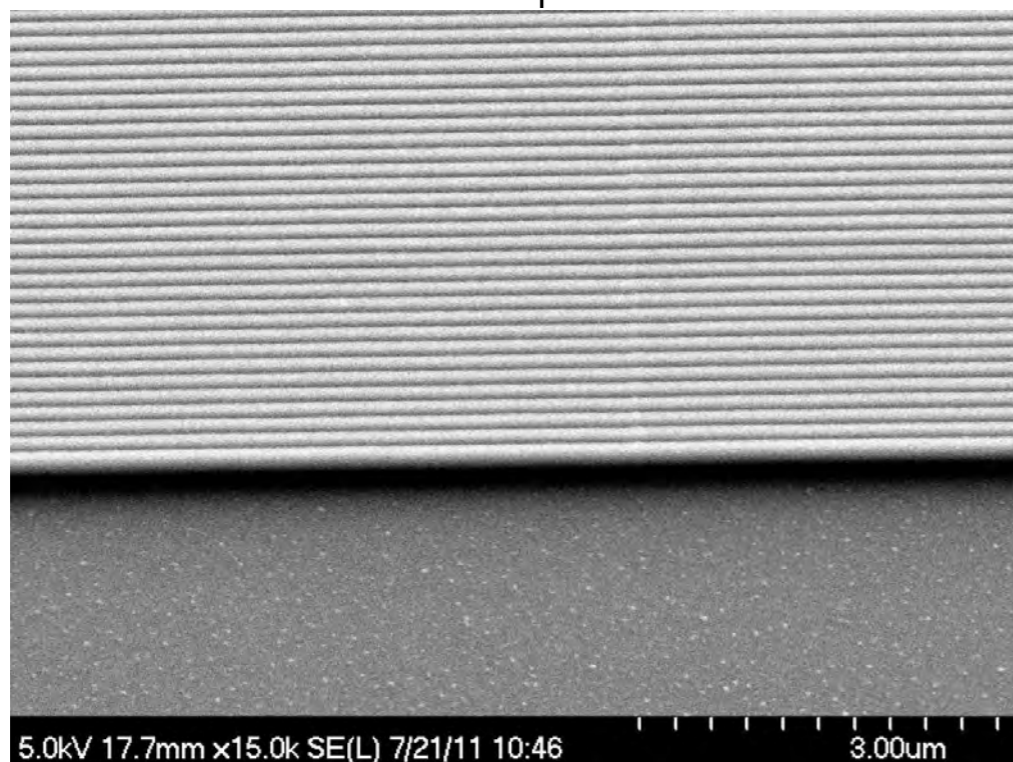
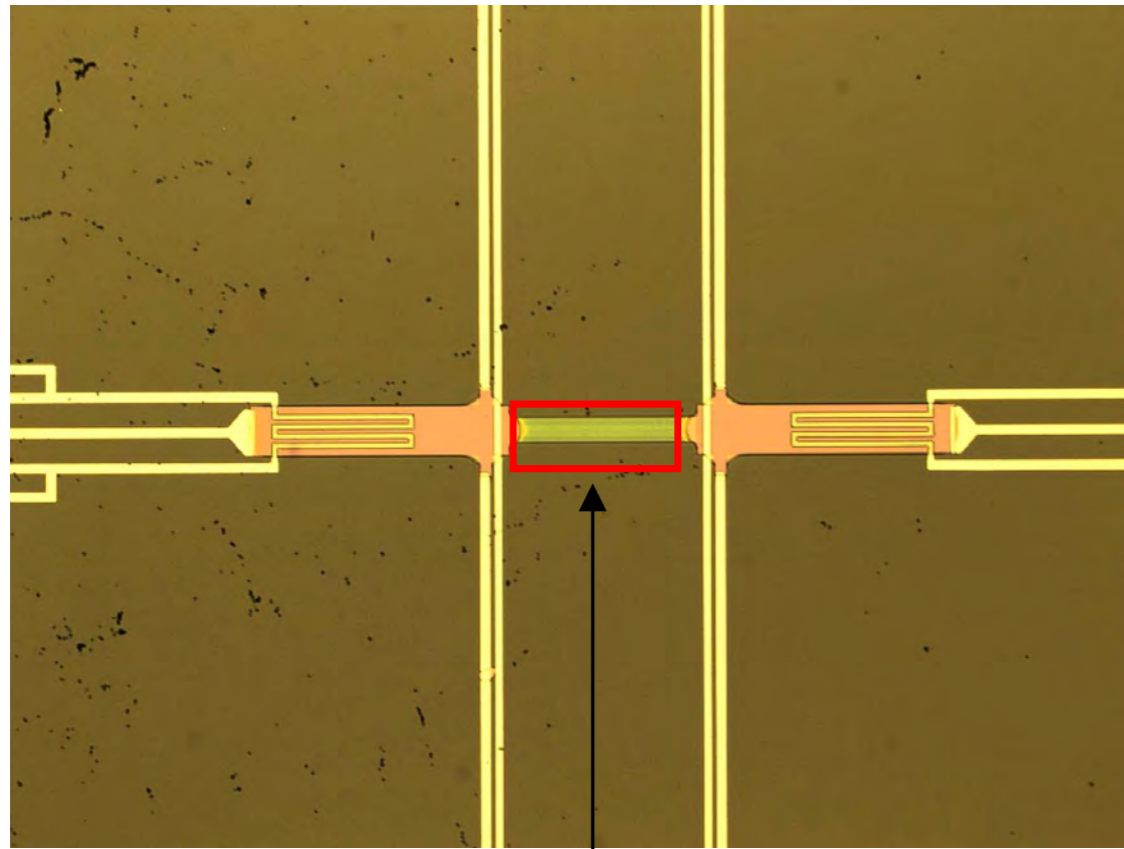


## TEM & XRD characterisation of 2D superlattice designs



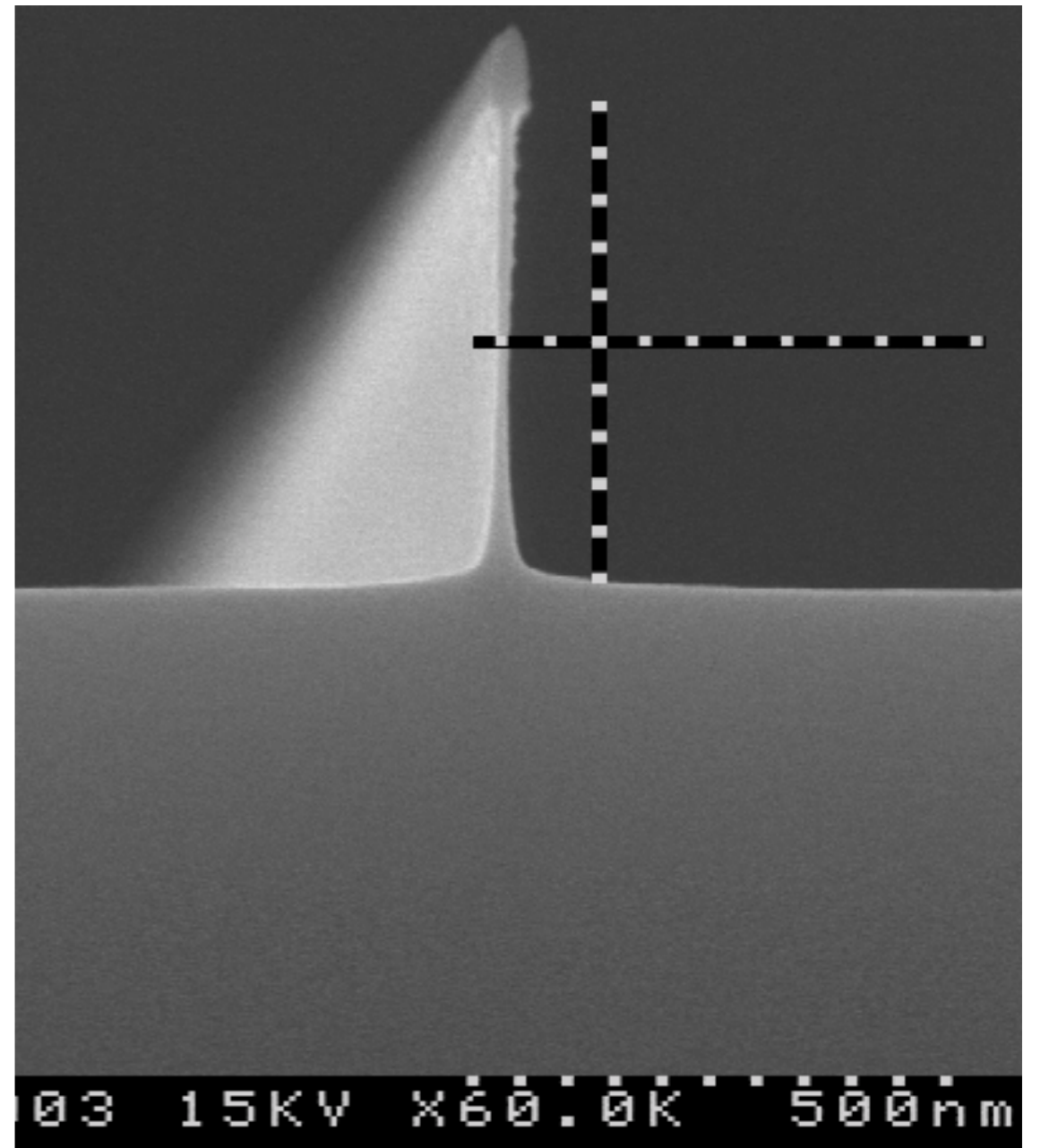


## Lateral Nanowires

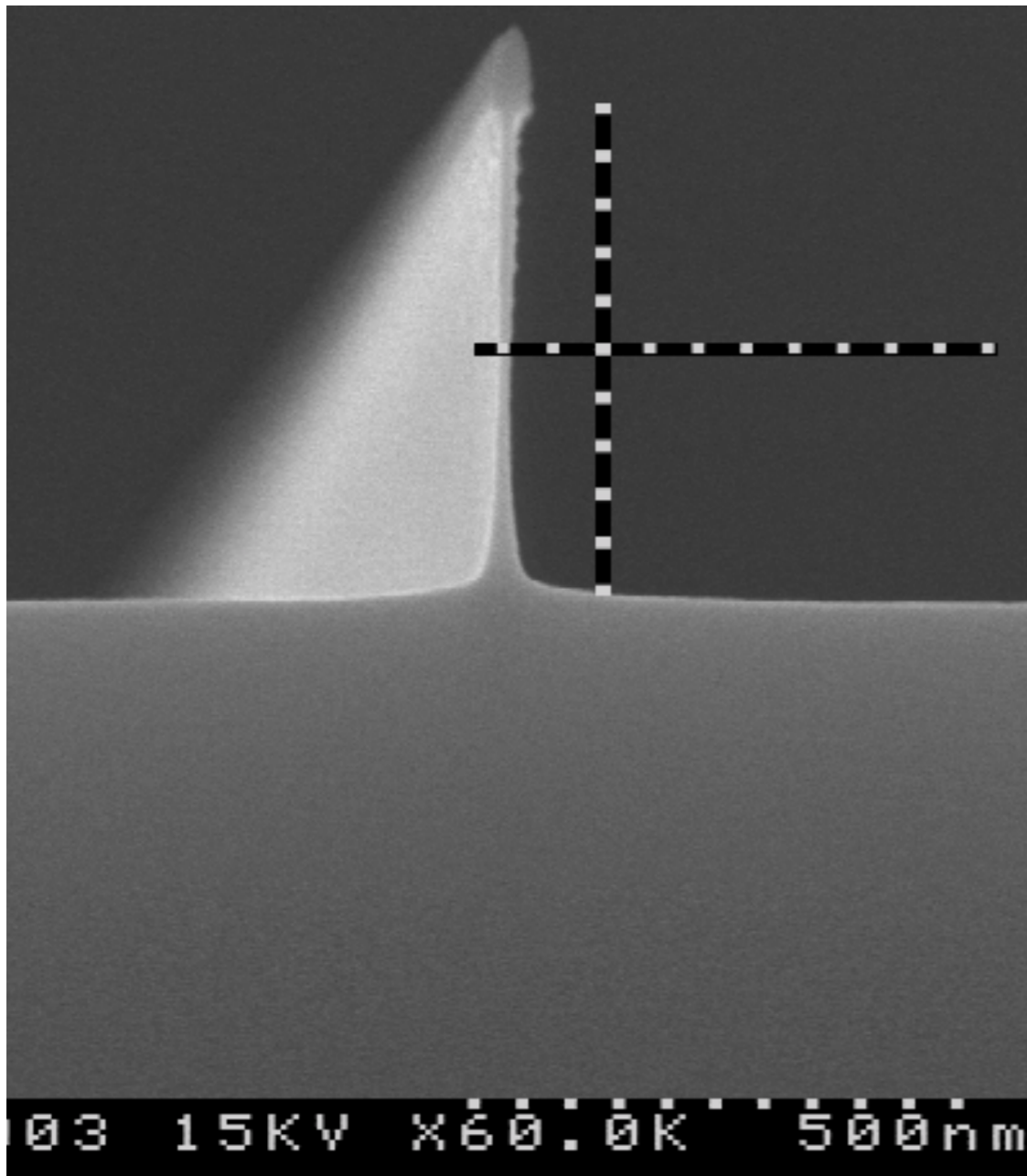


## Vertical Nanowires

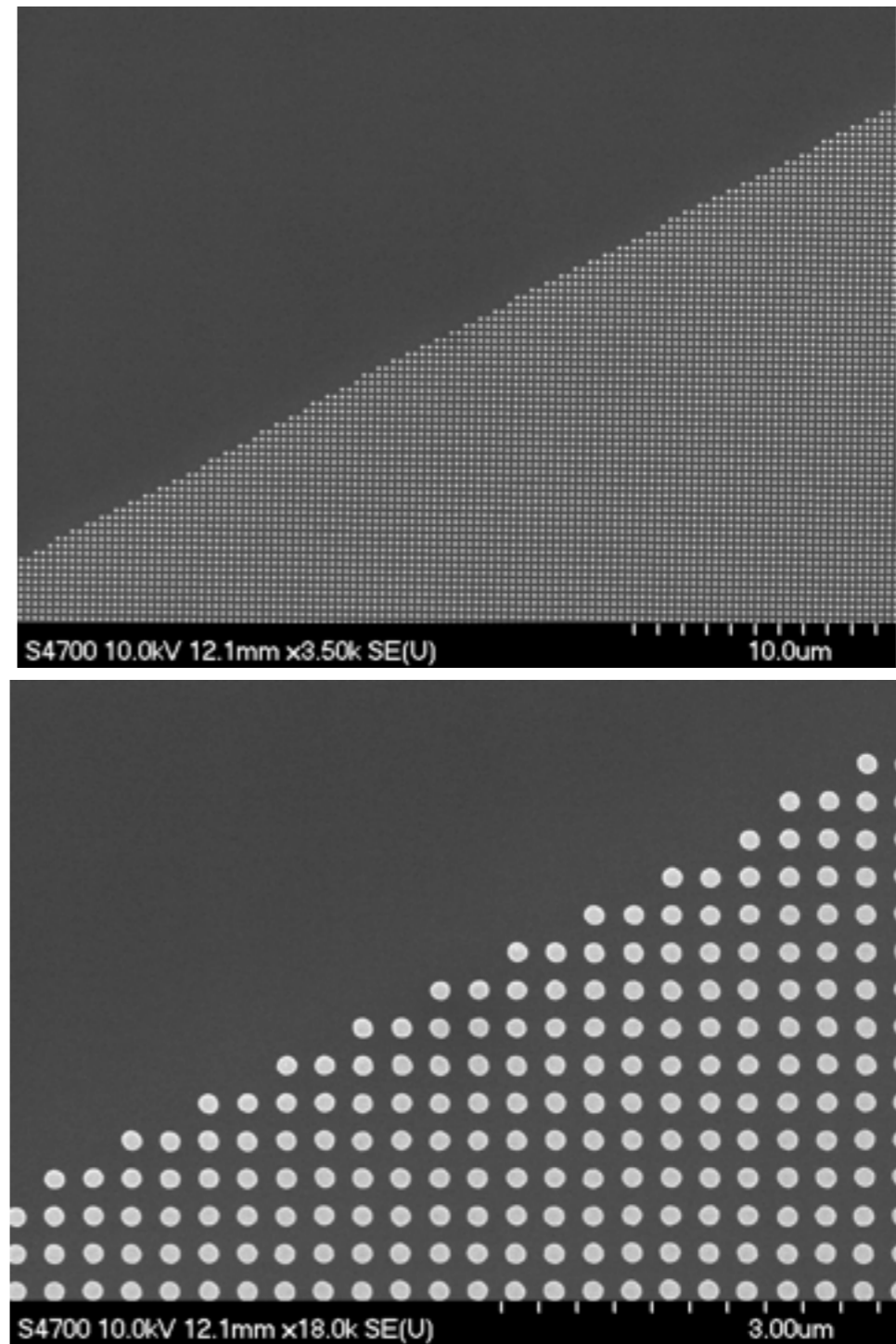
10 nm wide  
500 nm tall  
Si nanowire



**10 nm wide  
500 nm tall  
Si nanowire**



**57,600,000,000 Si pillars of  
40 nm diameter**



 Techniques towards cheap manufacture also being investigated

# Summary

- **Waste heat is everywhere → enormous number of applications**
- **Low dimensional structures are yet to demonstrate the predicted increases in  $\alpha$  due to DOS**
- **Reducing  $\kappa_{ph}$  faster than  $\sigma$  has been the most successful approach to improving ZT to date**
- **Heterointerface scattering of phonons has been successful in reducing  $\kappa$**
- **TE materials and generators are not optimised → there is plenty of room for innovation**

# Further Reading

- D.M. Rowe (Ed.), *“Thermoelectrics Handbook: Macro to Nano”*  
CRC Taylor and Francis (2006) ISBN 0-8494-2264-2
- G.S. Nolas, J. Sharp and H.J. Goldsmid *“Thermoelectrics: Basic Principles and New Materials Development”* (2001) ISBN 3-540-41245-X
- M.S. Dresselhaus et al. *“New directions for low-dimensional thermoelectric materials”* Adv. Mat. 19, 1043 (2007)

## Further Information

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**<http://www.greensilicon.eu/GREENSilicon/index.html>**